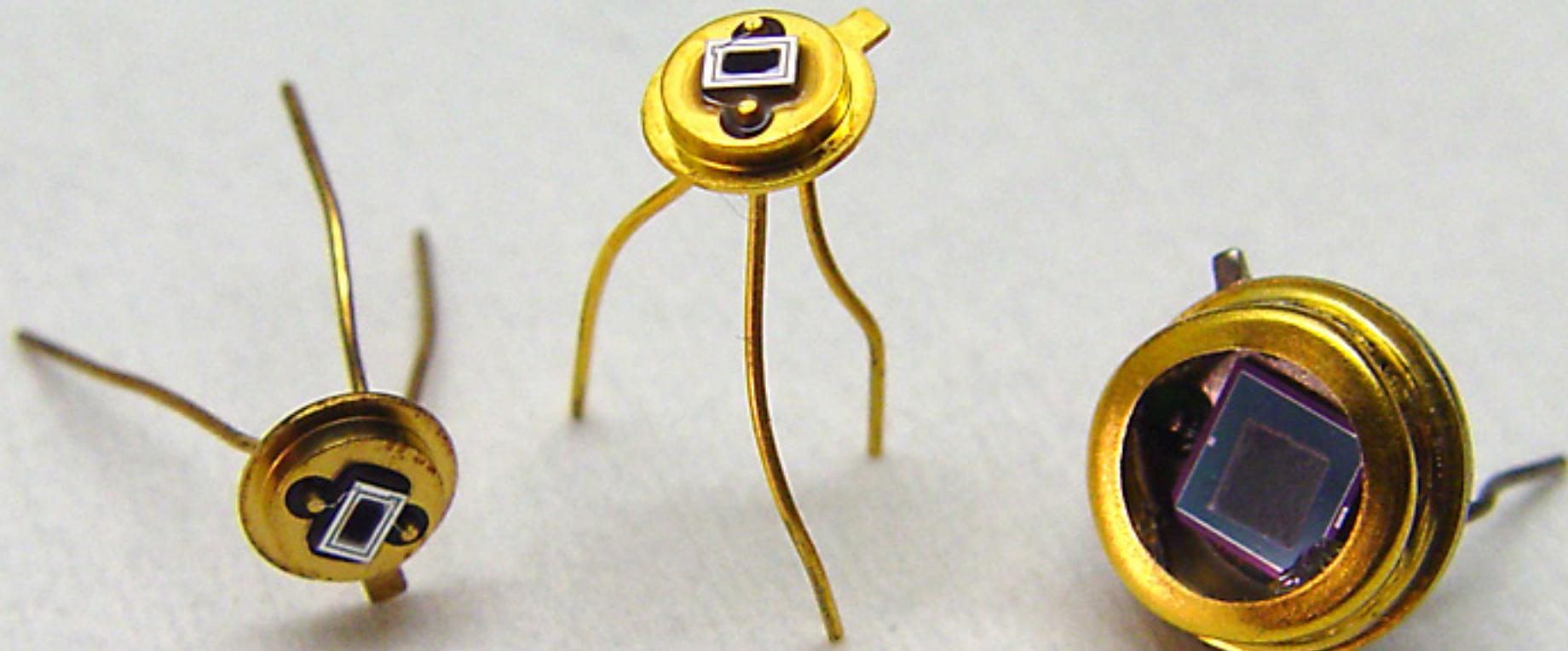


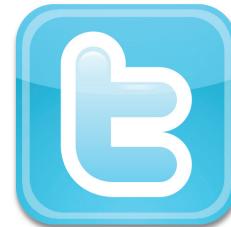
Ultrashort lasers to increase efficiency in solar energy harvesting via intermediate states



2014 High Power Laser Ablation Symposium
Santa Fe, NM 23 April 2014



Ultrashort lasers to increase efficiency in solar energy harvesting via intermediate states



@eric_mazur

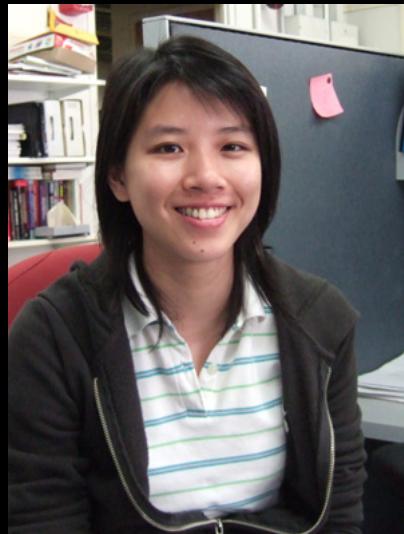


2014 High Power Laser Ablation Symposium
Santa Fe, NM 23 April 2014





Renee Sher



Yu-Ting Lin



Kasey Philips



Ben Franta



eric_mazur

and also....

Hemi Gandhi
Alexander Raymond
Marc Winkler
Eric Diebold
Haifei Albert Zhang
Dr. Brian Tull
Dr. Jim Carey (SiOnyx)
Prof. Tsing-Hua Her (UNC Charlotte)
Dr. Shrenik Deliwala
Dr. Richard Finlay
Dr. Michael Sheehy
Dr. Claudia Wu
Dr. Rebecca Younkin
Prof. Catherine Crouch (Swarthmore)
Prof. Mengyan Shen (Lowell U)
Prof. Li Zhao (Fudan U)

Prof. Alan Aspuru-Guzik
Prof. Michael Aziz
Prof. Michael Brenner
Prof. Cynthia Friend
Prof. Howard Stone

Dr. Martin Pralle (SiOnyx)
and everyone else at SiOnyx...

Prof. Tonio Buonassisi (MIT)
Prof. Silvija Gradecak (MIT)
Prof. Jeff Grossman (MIT)
Dr. Bonna Newman (MIT)
Joe Sullivan (MIT)
Matthew Smith (MIT)

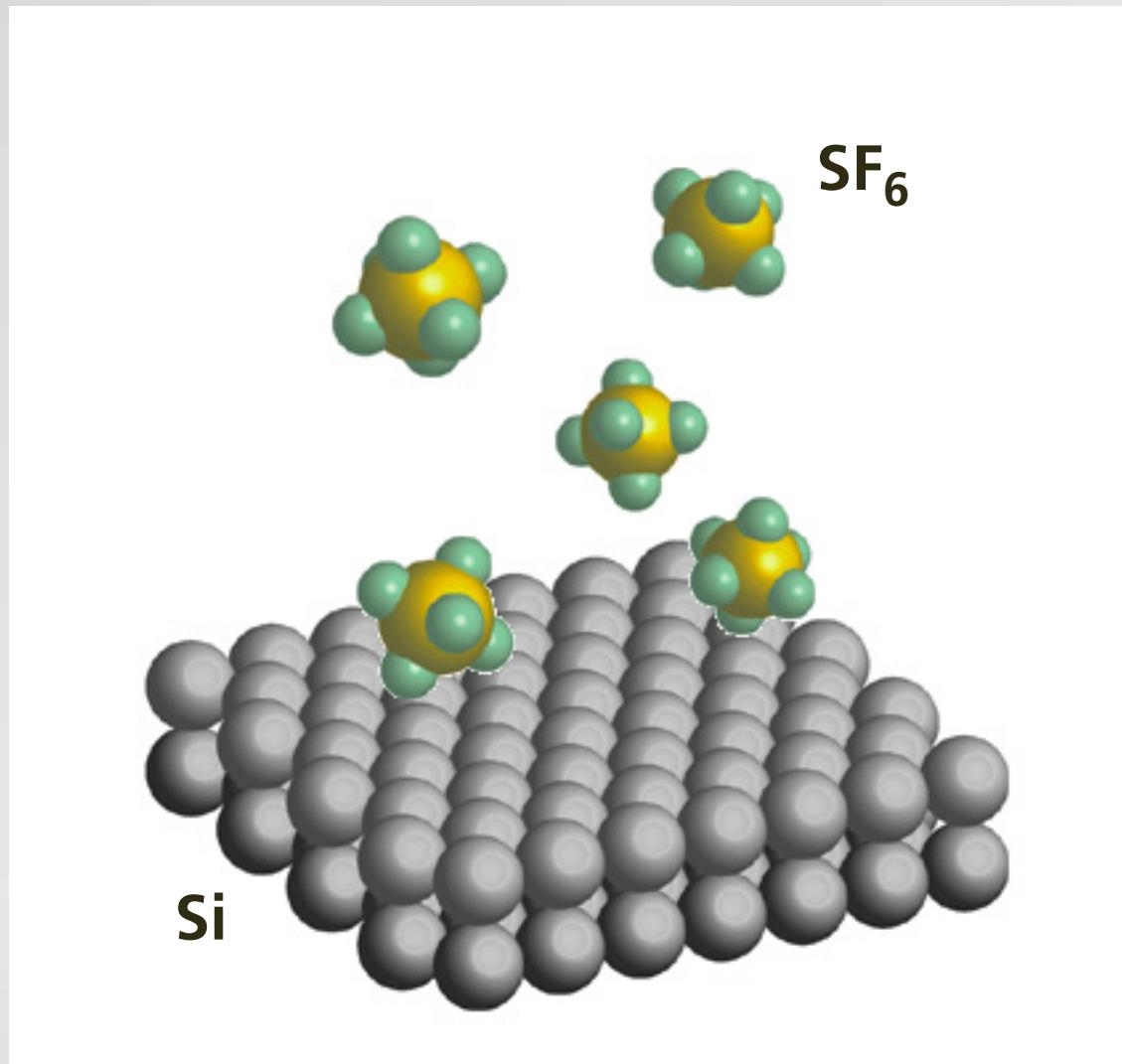
Prof. Augustinus Asenbaum (Vienna)

Dr. François Génin (LLNL)
Mark Wall (LLNL)

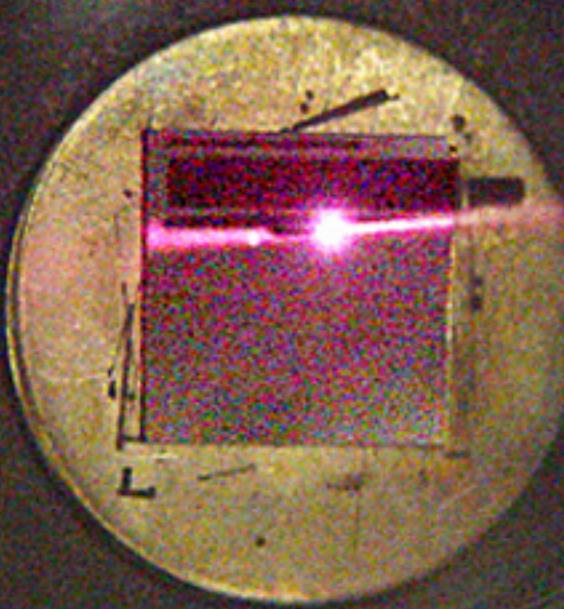
Dr. Richard Farrell (RMD)
Dr. Arieh Karger (RMD)
Dr. Richard Meyers (RMD)

Dr. Pat Maloney (NVSED)

Dr. Jeffrey Warrander (ARDEC)

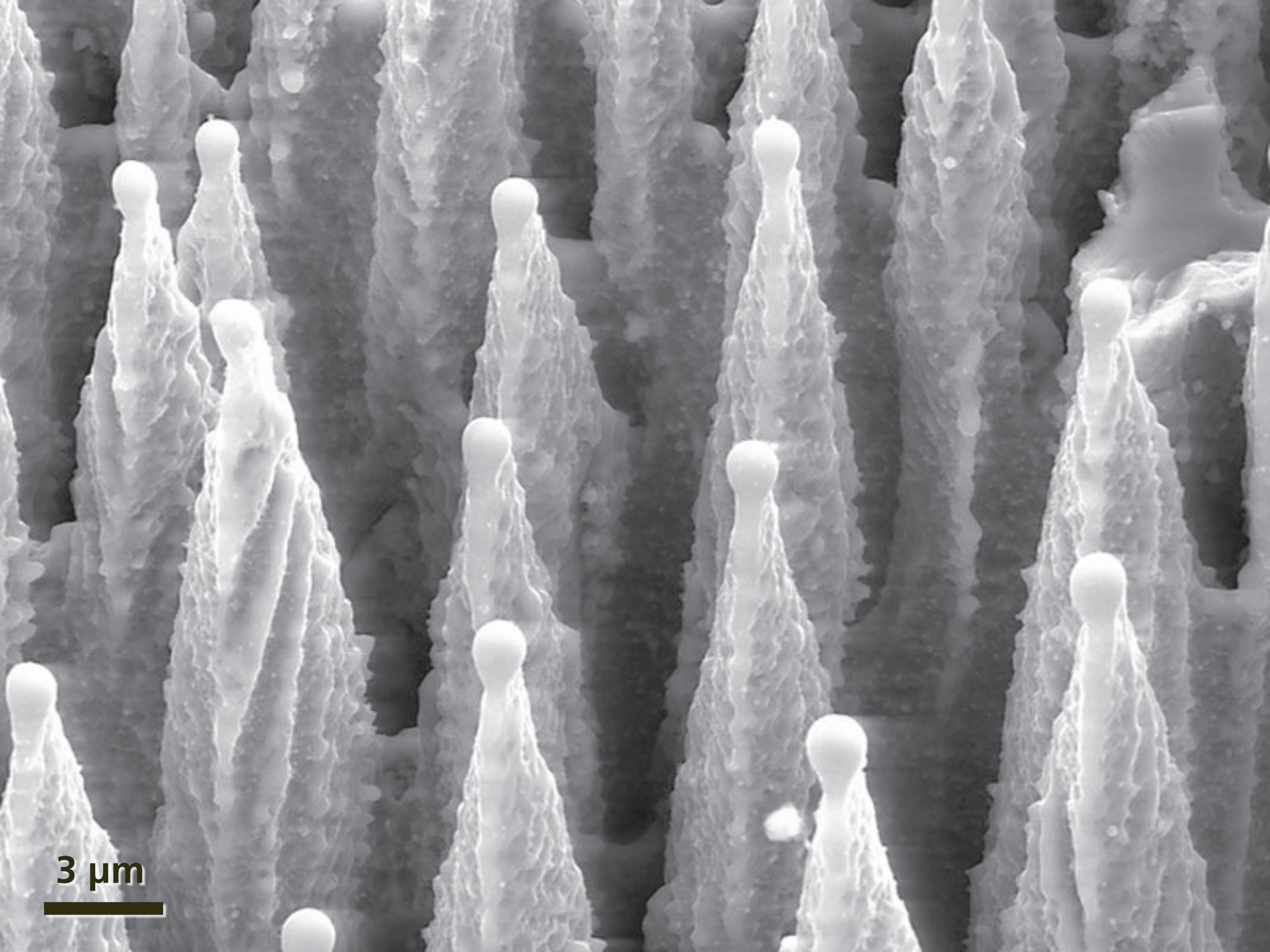


irradiate with 100-fs 10 kJ/m² pulses



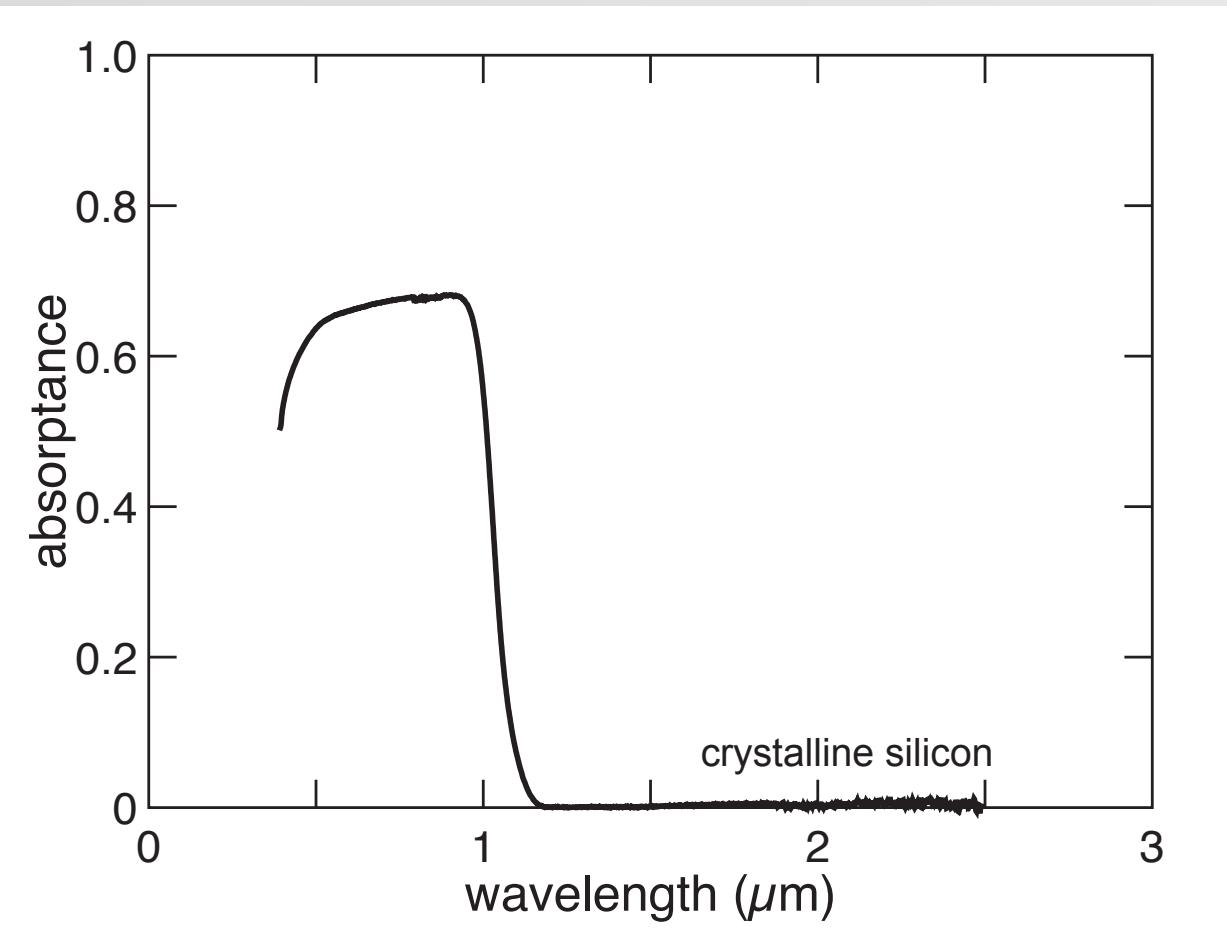


"black silicon"

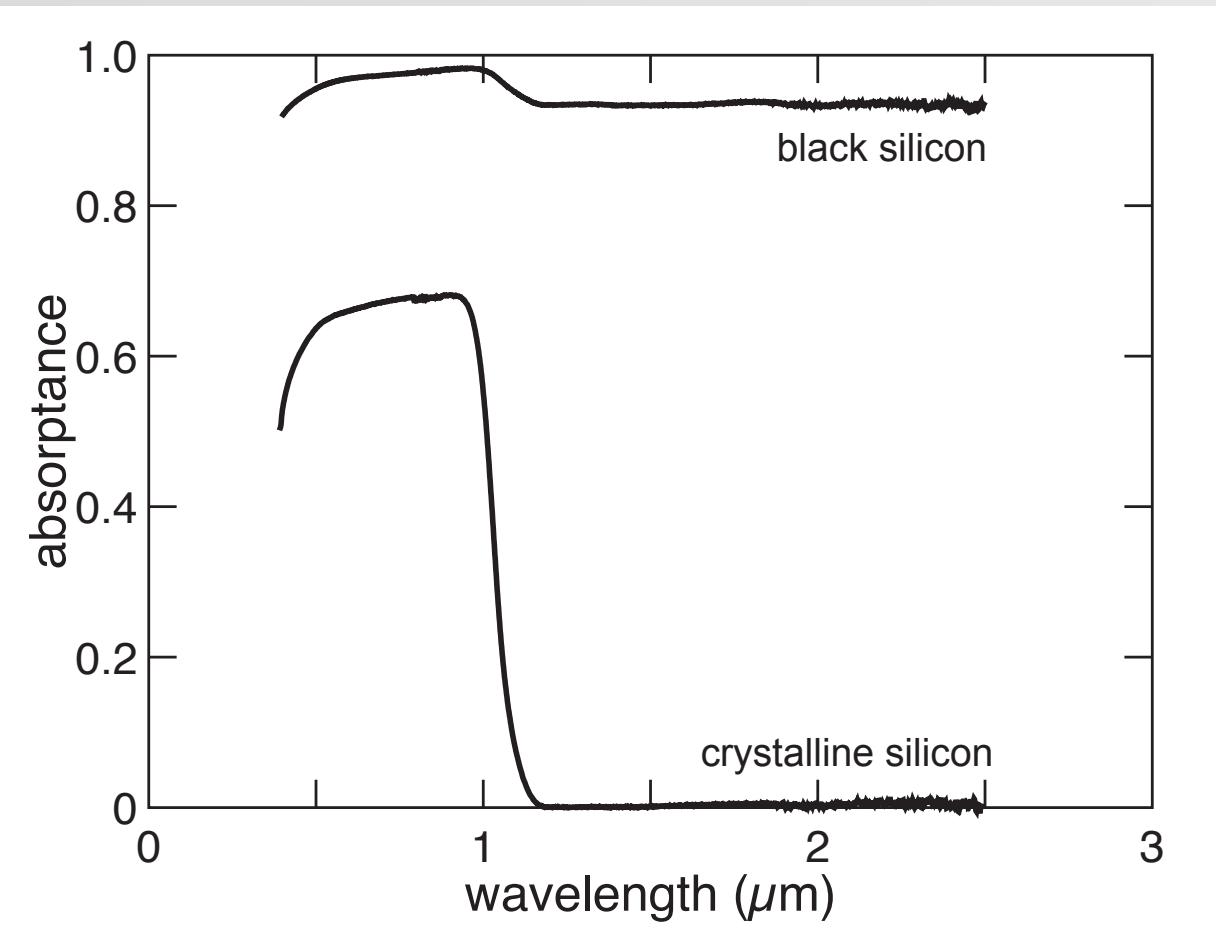


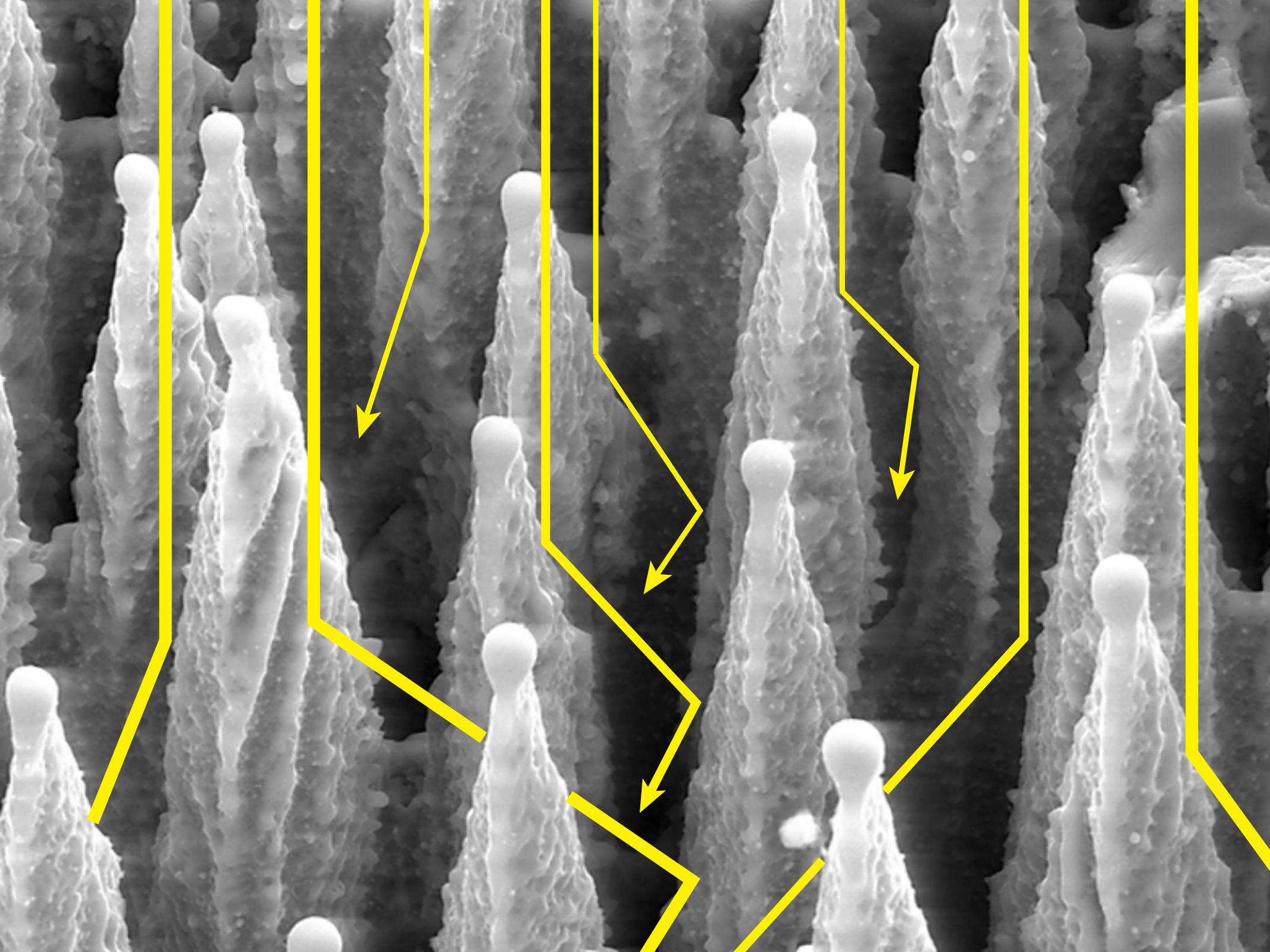
3 μm

absorptance ($1 - R_{int} - T_{int}$)

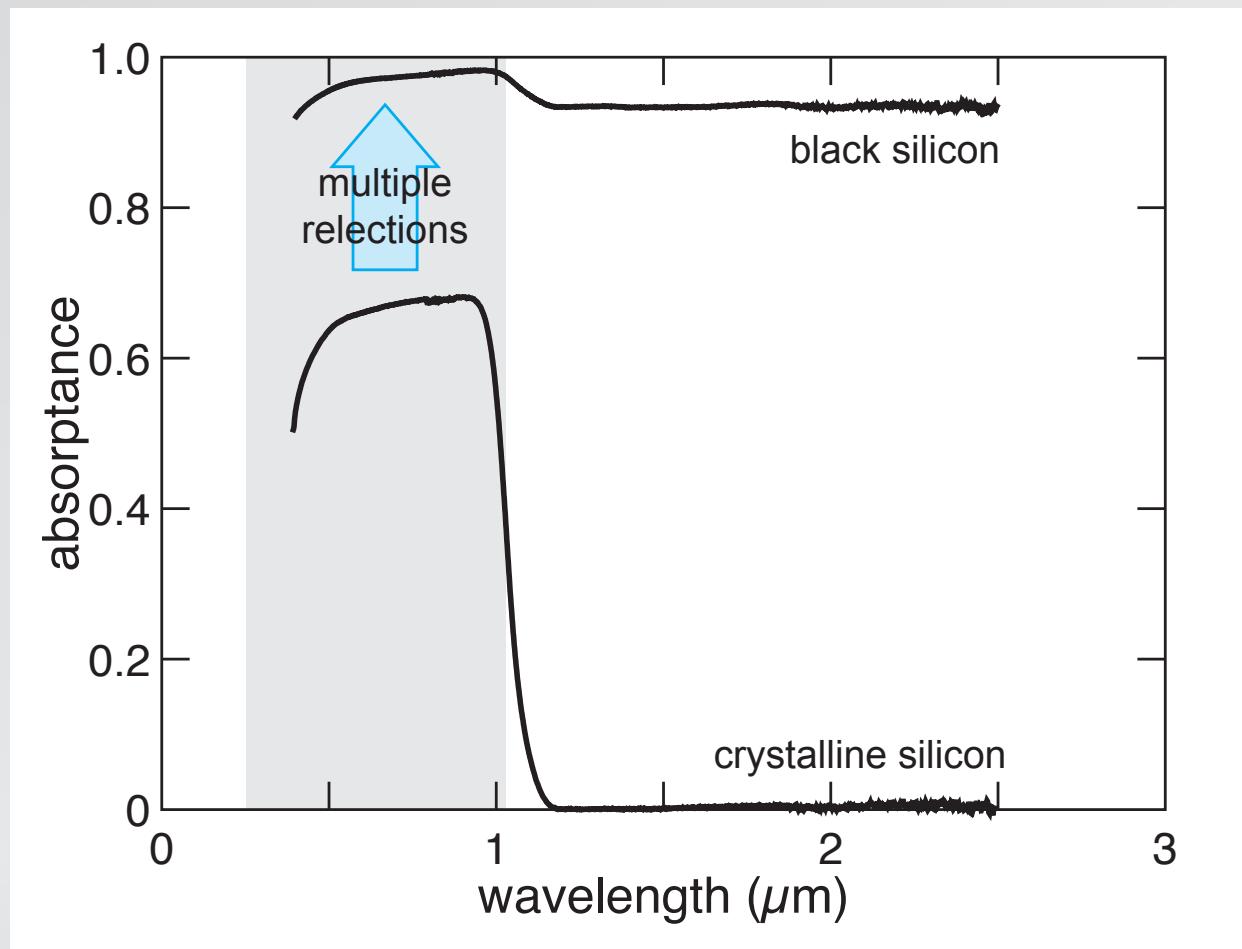


absorptance ($1 - R_{int} - T_{int}$)

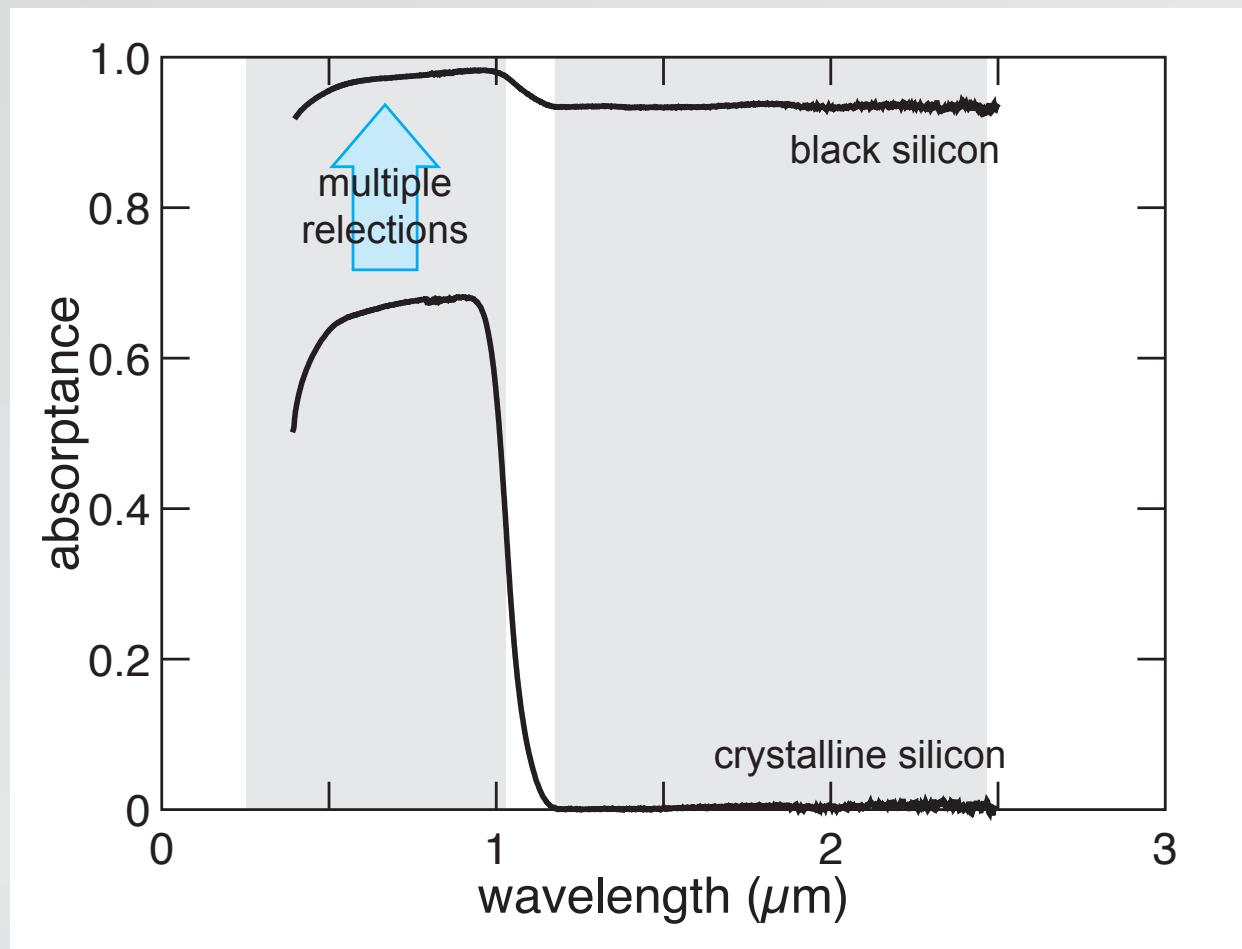




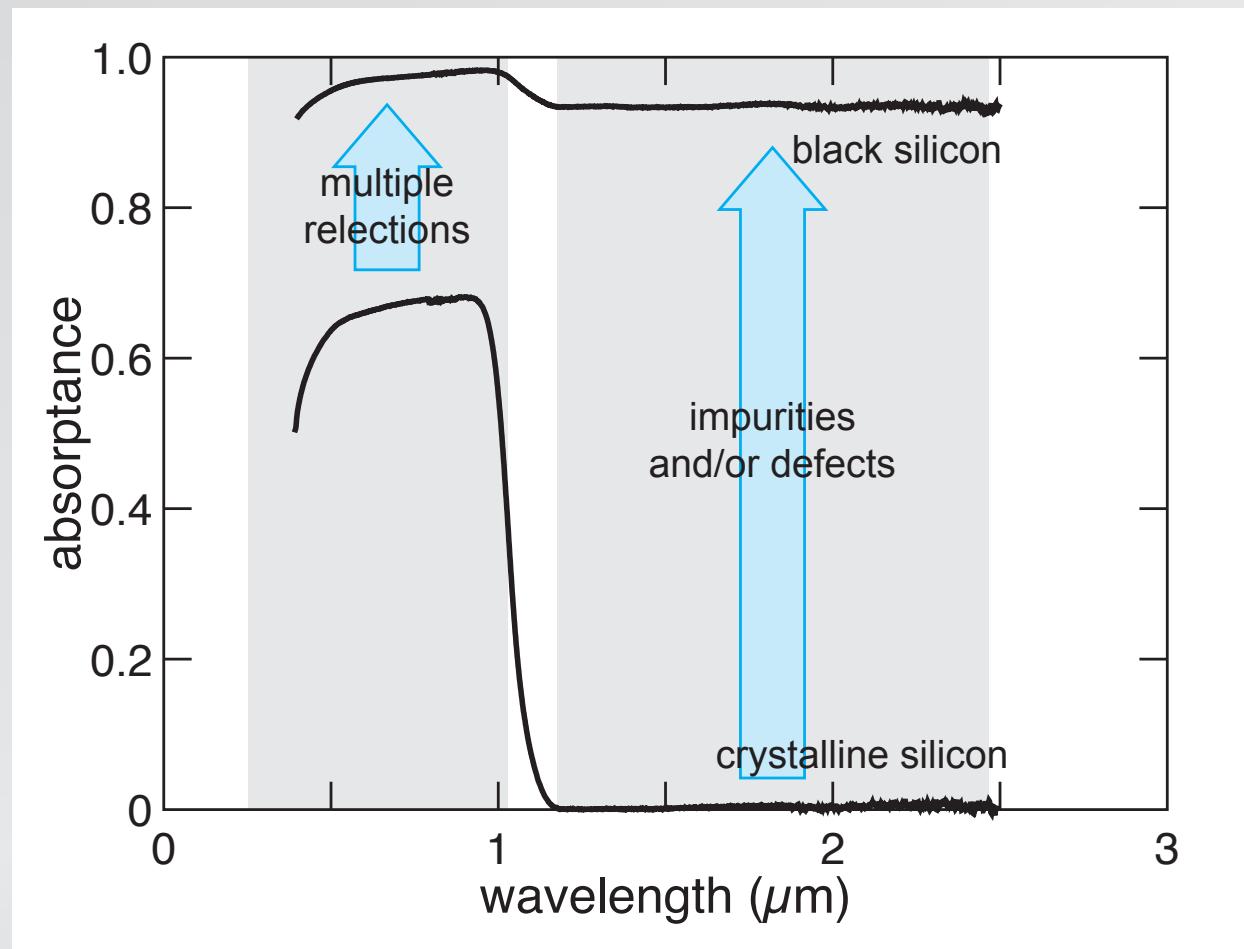
absorptance ($1 - R_{int} - T_{int}$)



absorptance ($1 - R_{int} - T_{int}$)

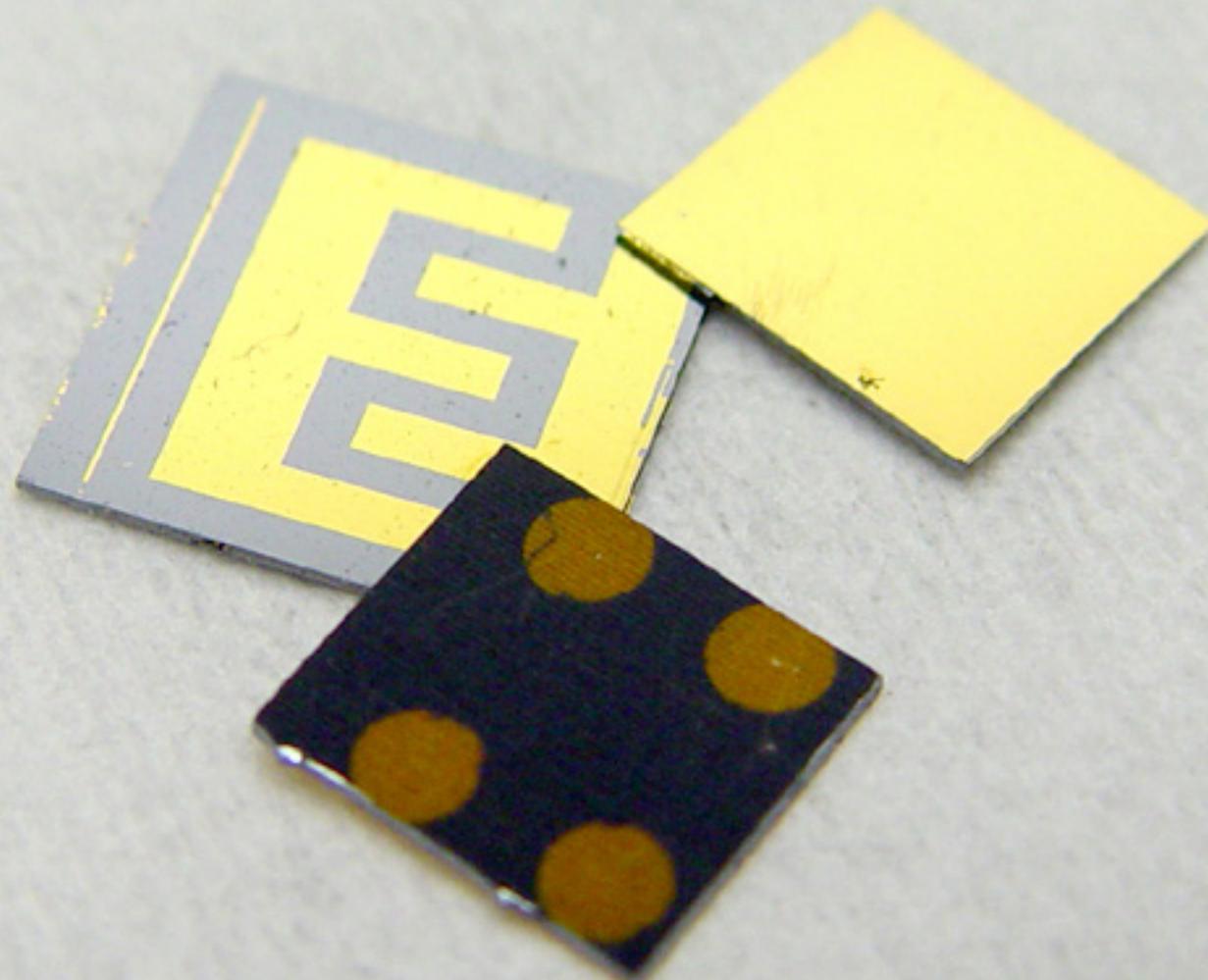


absorptance ($1 - R_{int} - T_{int}$)

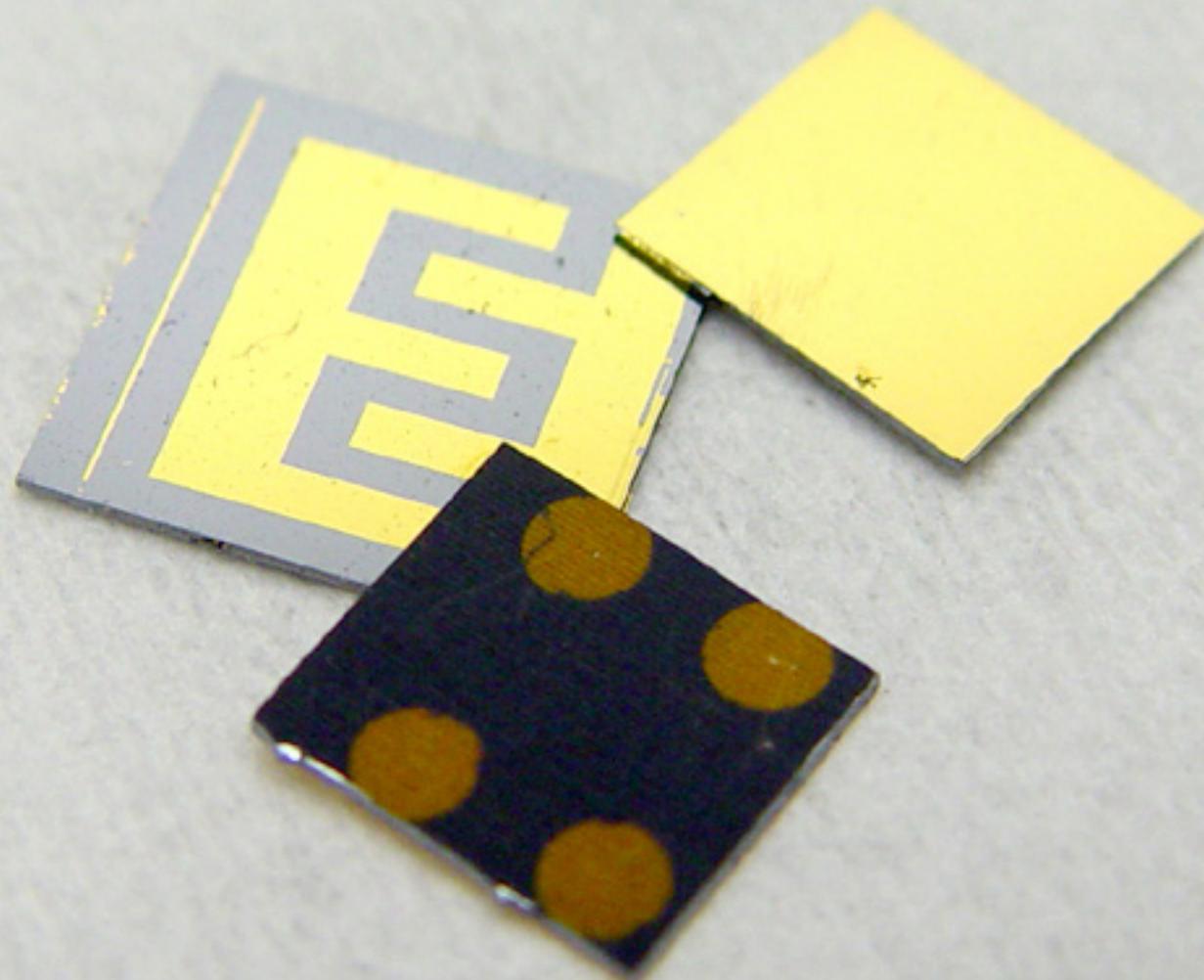


laser treatment causes:

- **surface structuring**
- **inclusion of dopants**

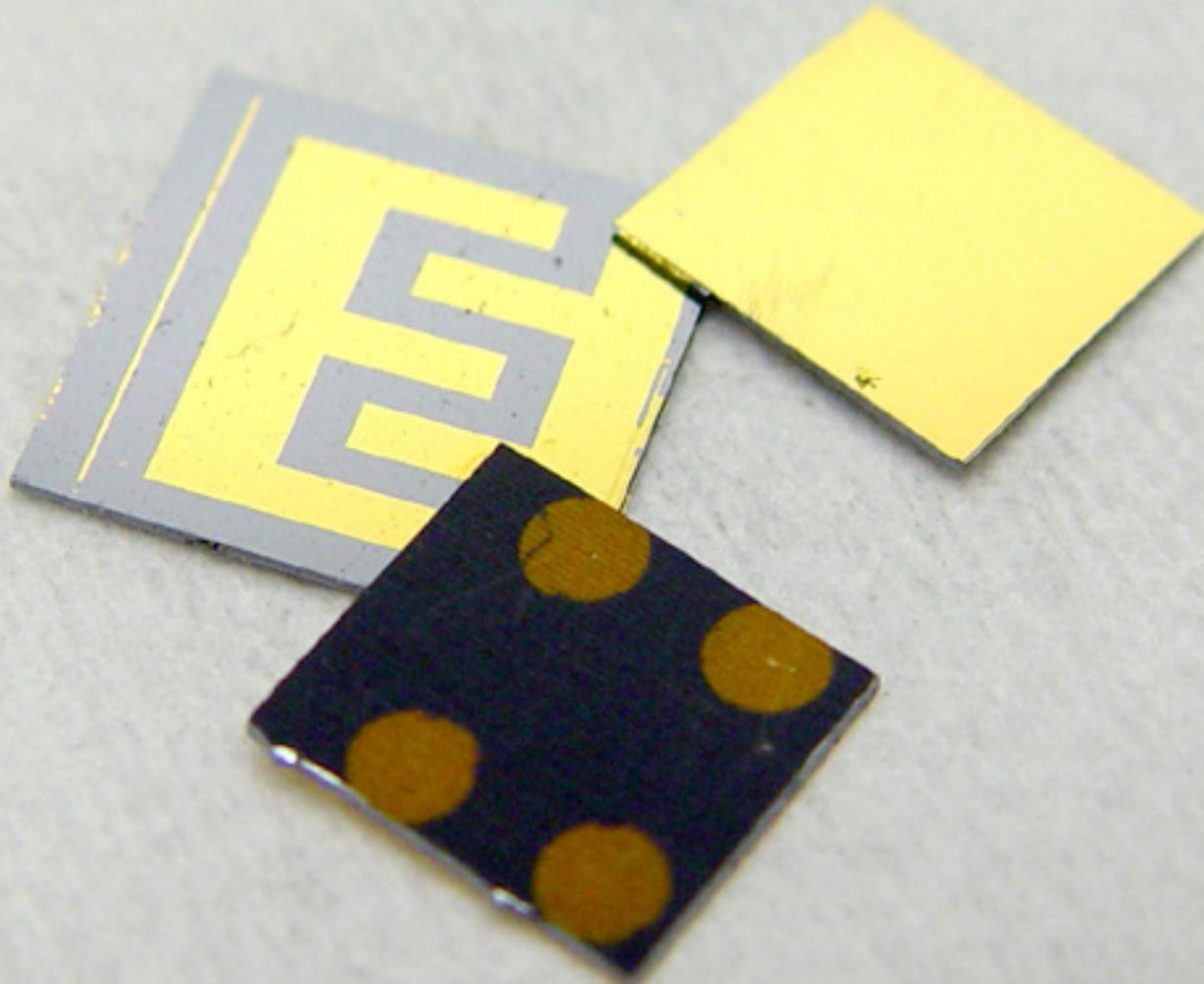


1 properties



1 properties

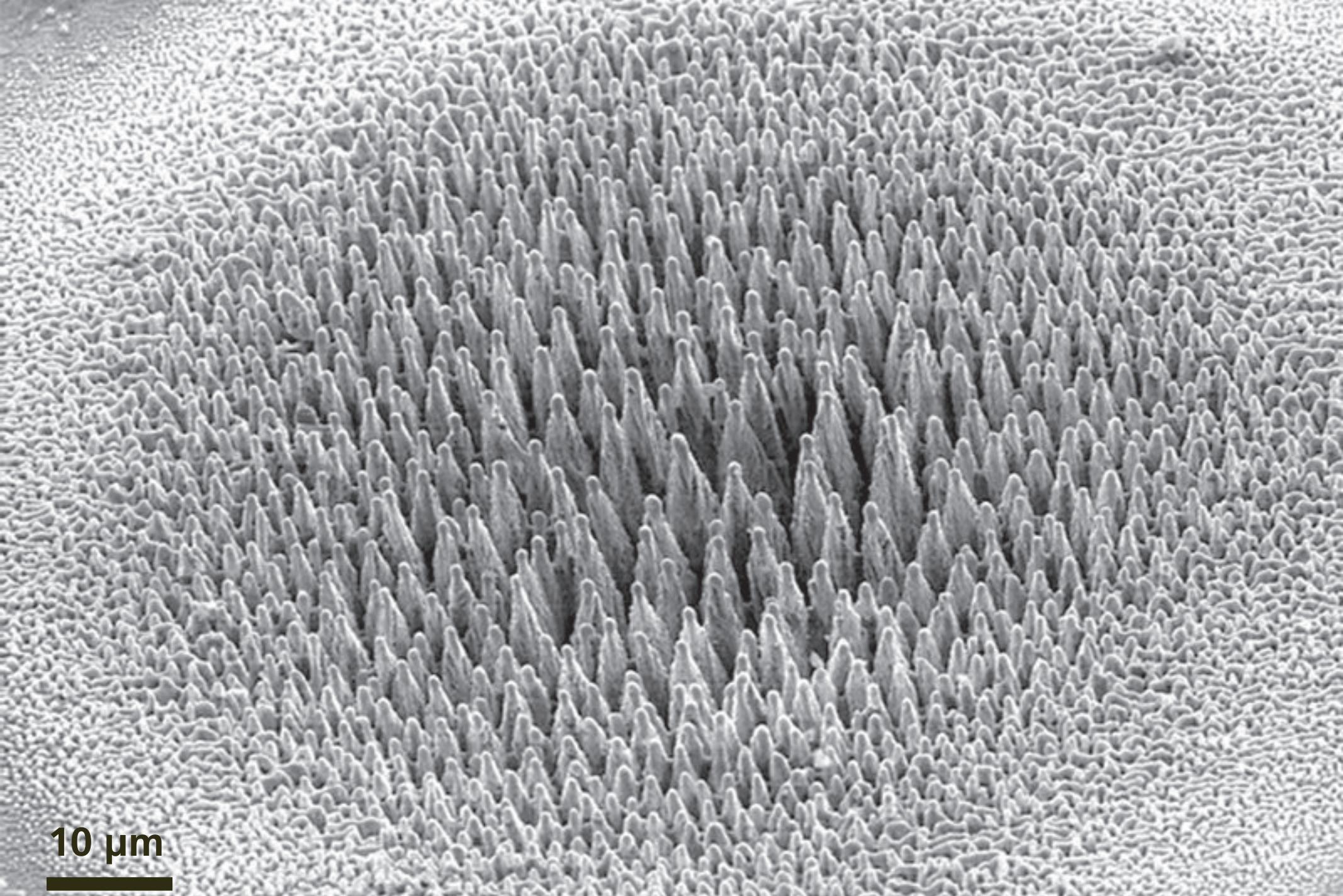
2 intermediate band



1 properties

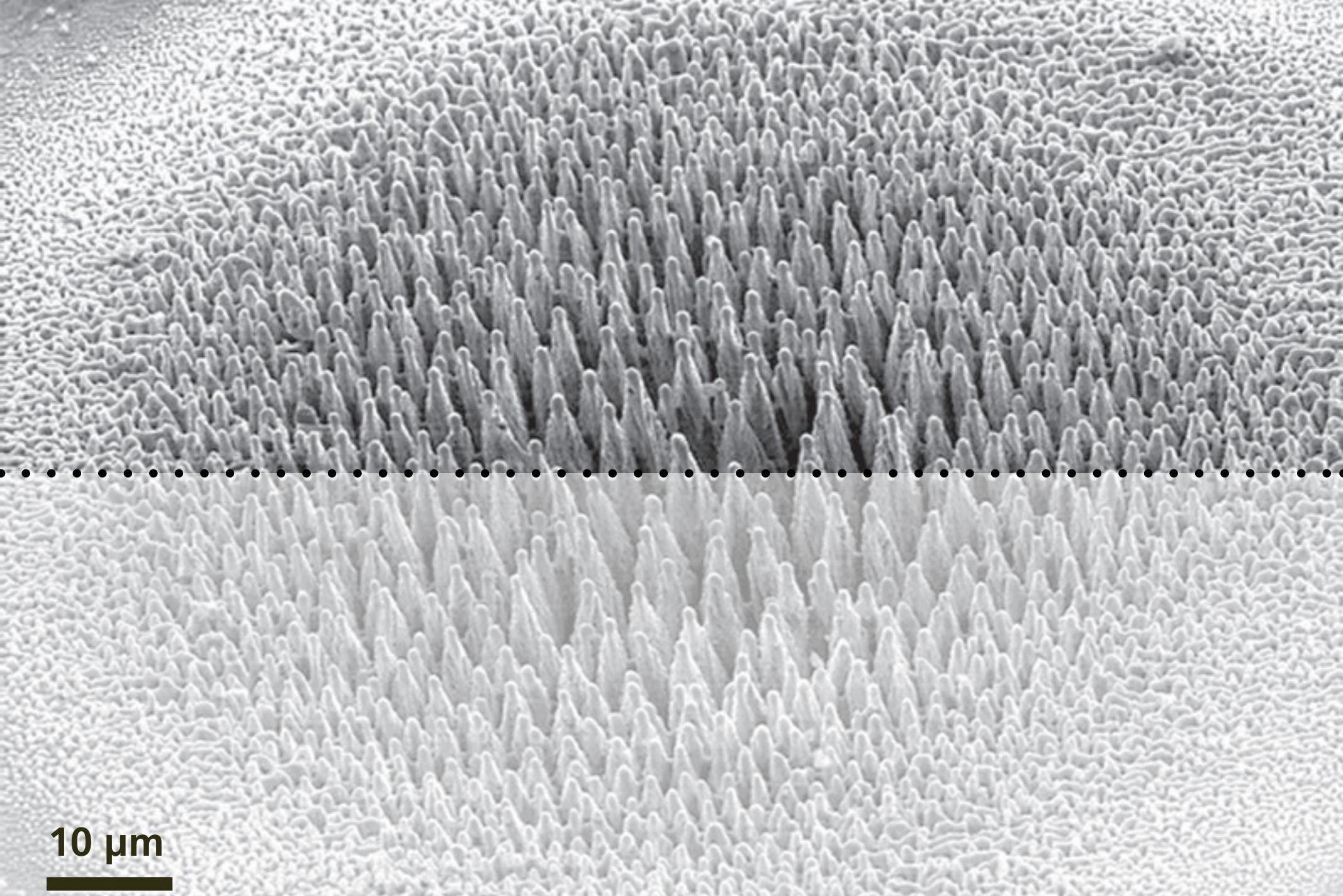
2 intermediate band

3 devices



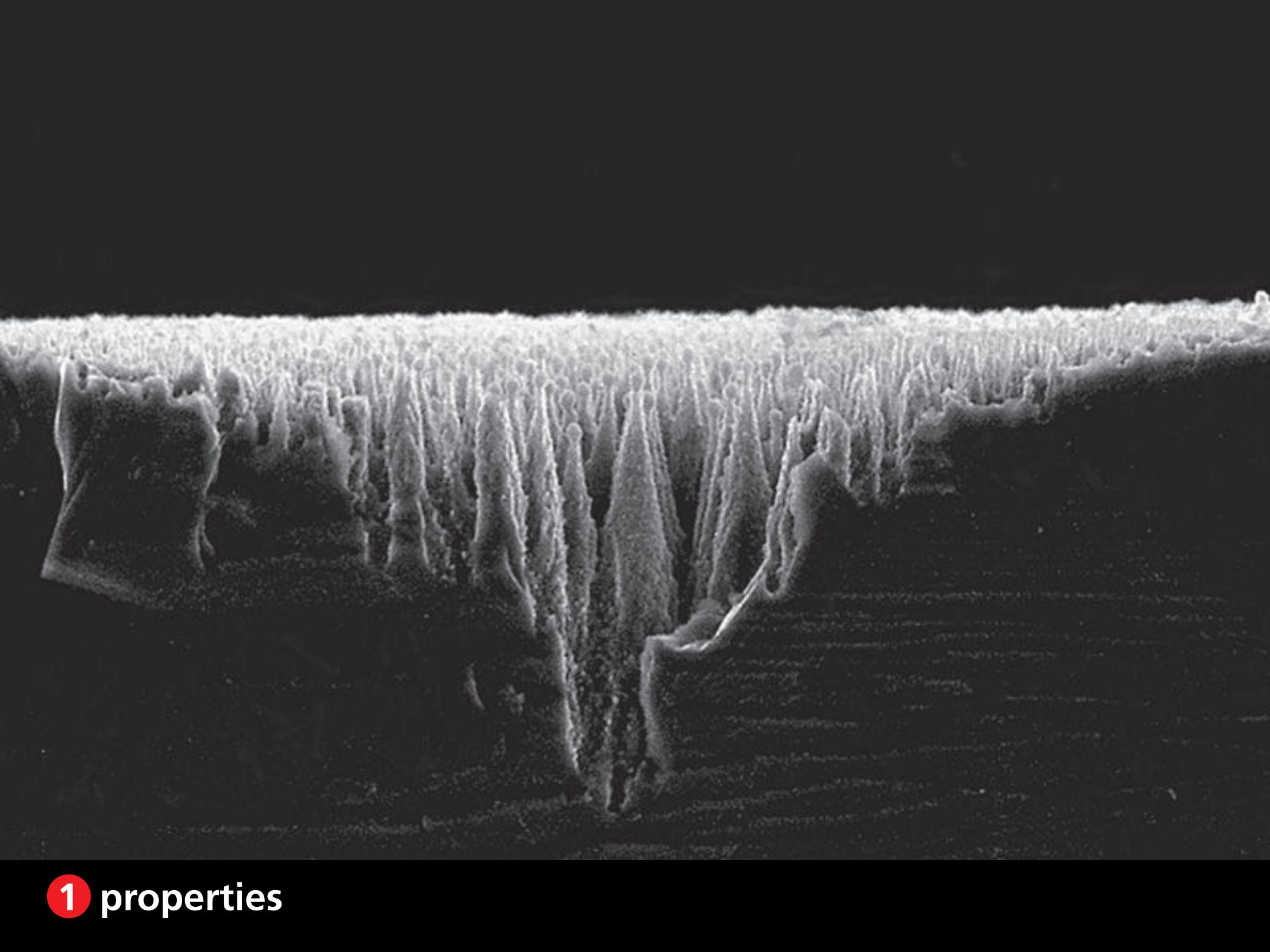
10 μm

1 properties

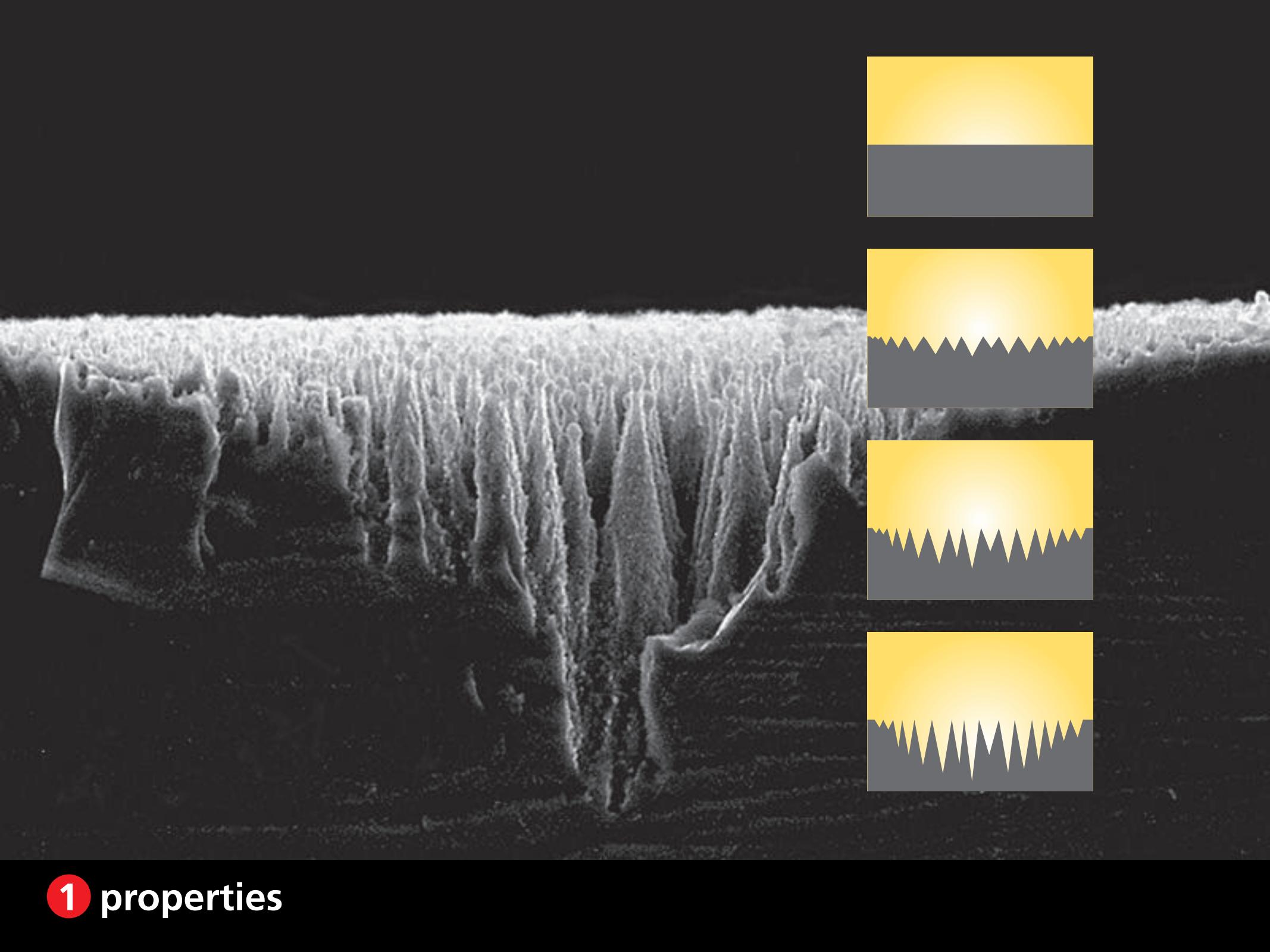


10 μm

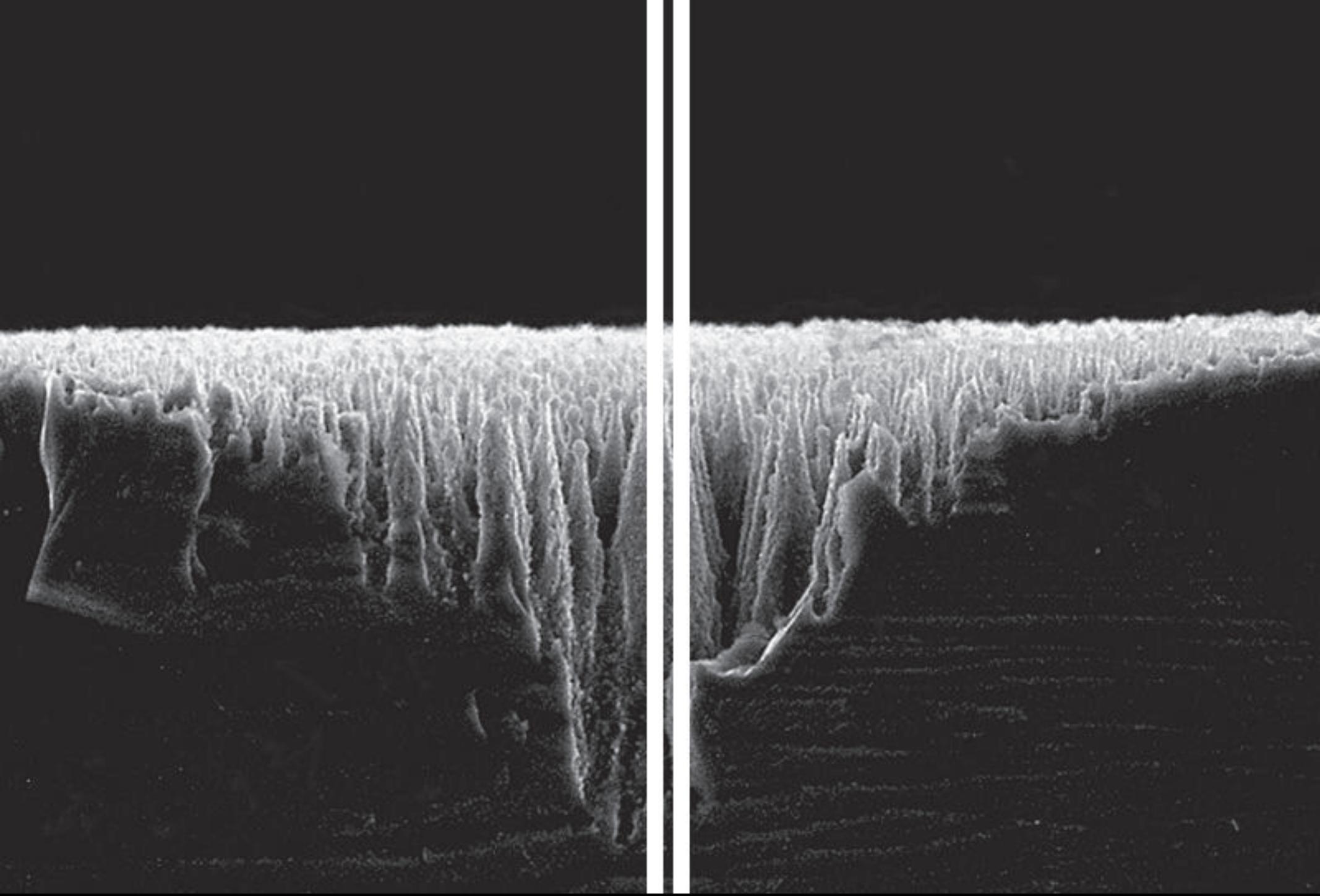
1 properties



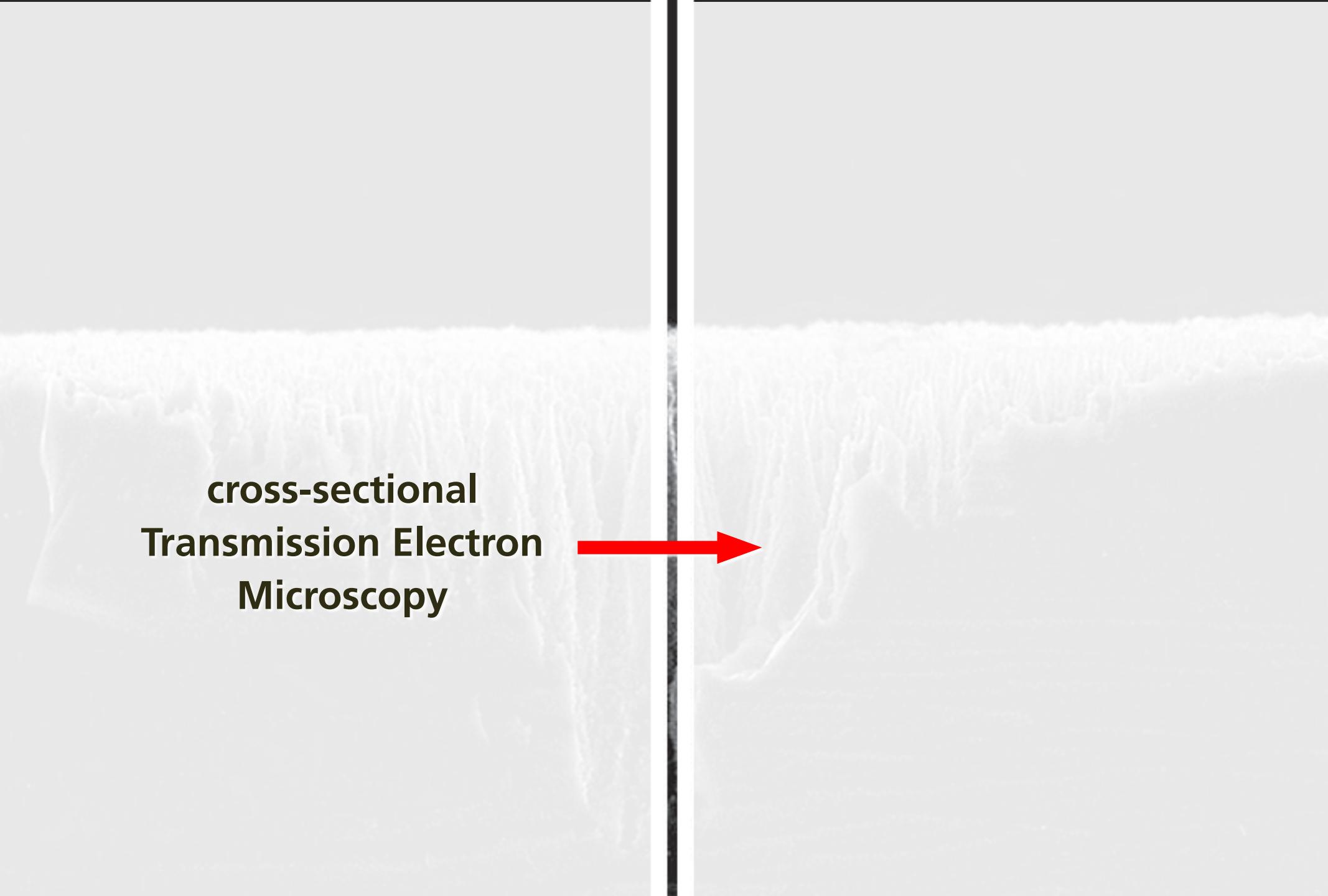
1 properties



1 properties



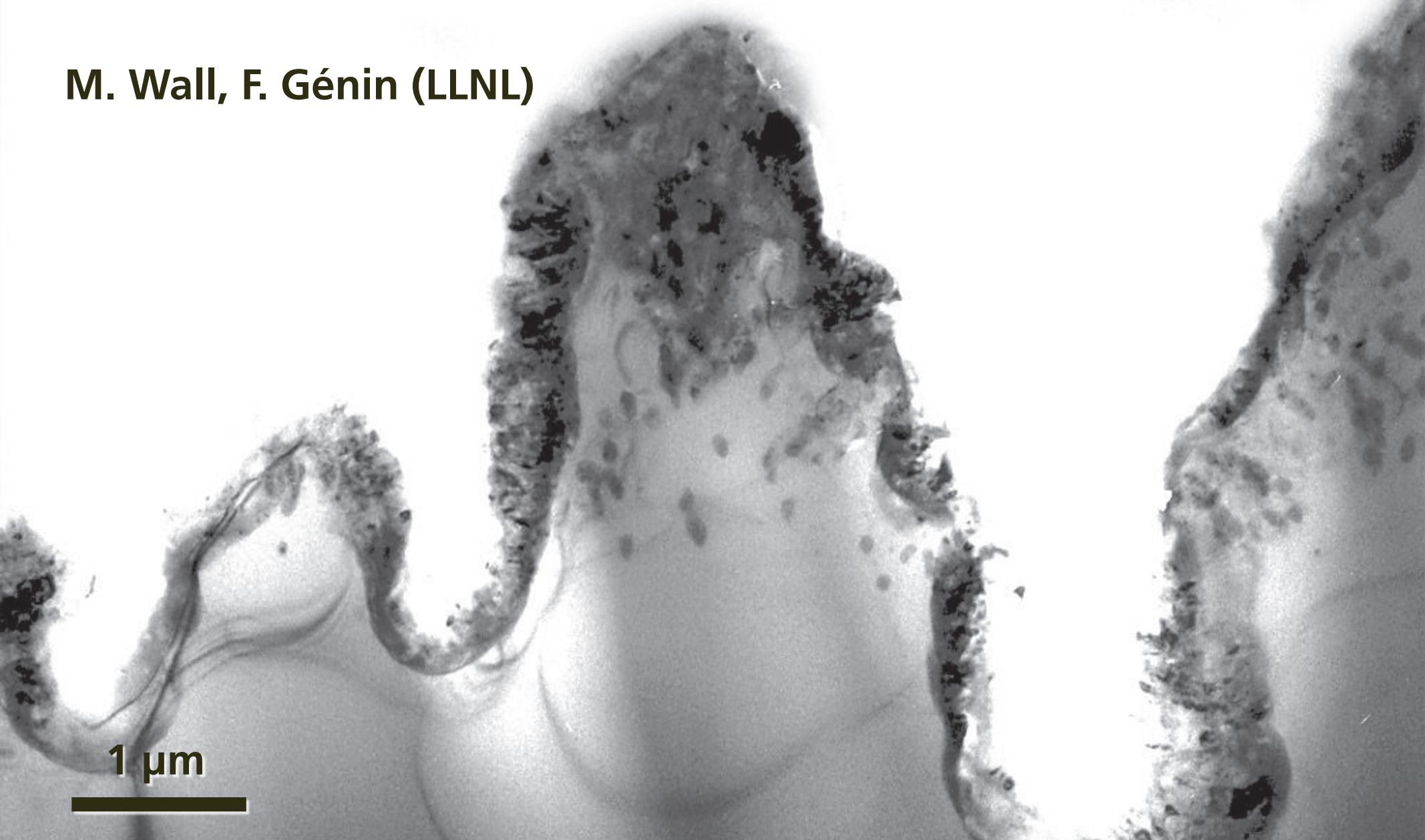
1 properties



**cross-sectional
Transmission Electron
Microscopy**



M. Wall, F. Génin (LLNL)



1 μm

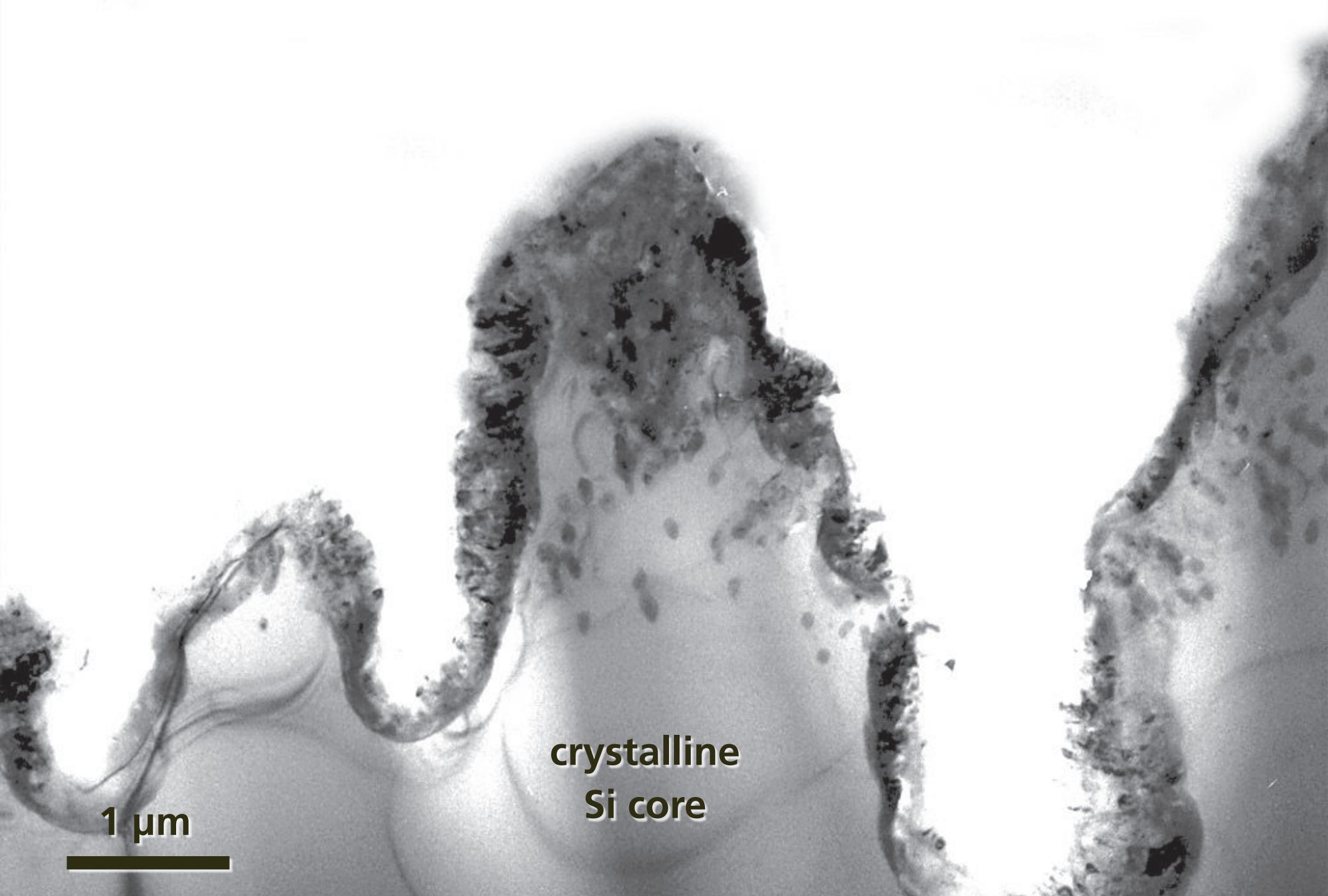
1 properties



**disordered
surface layer**

1 μm

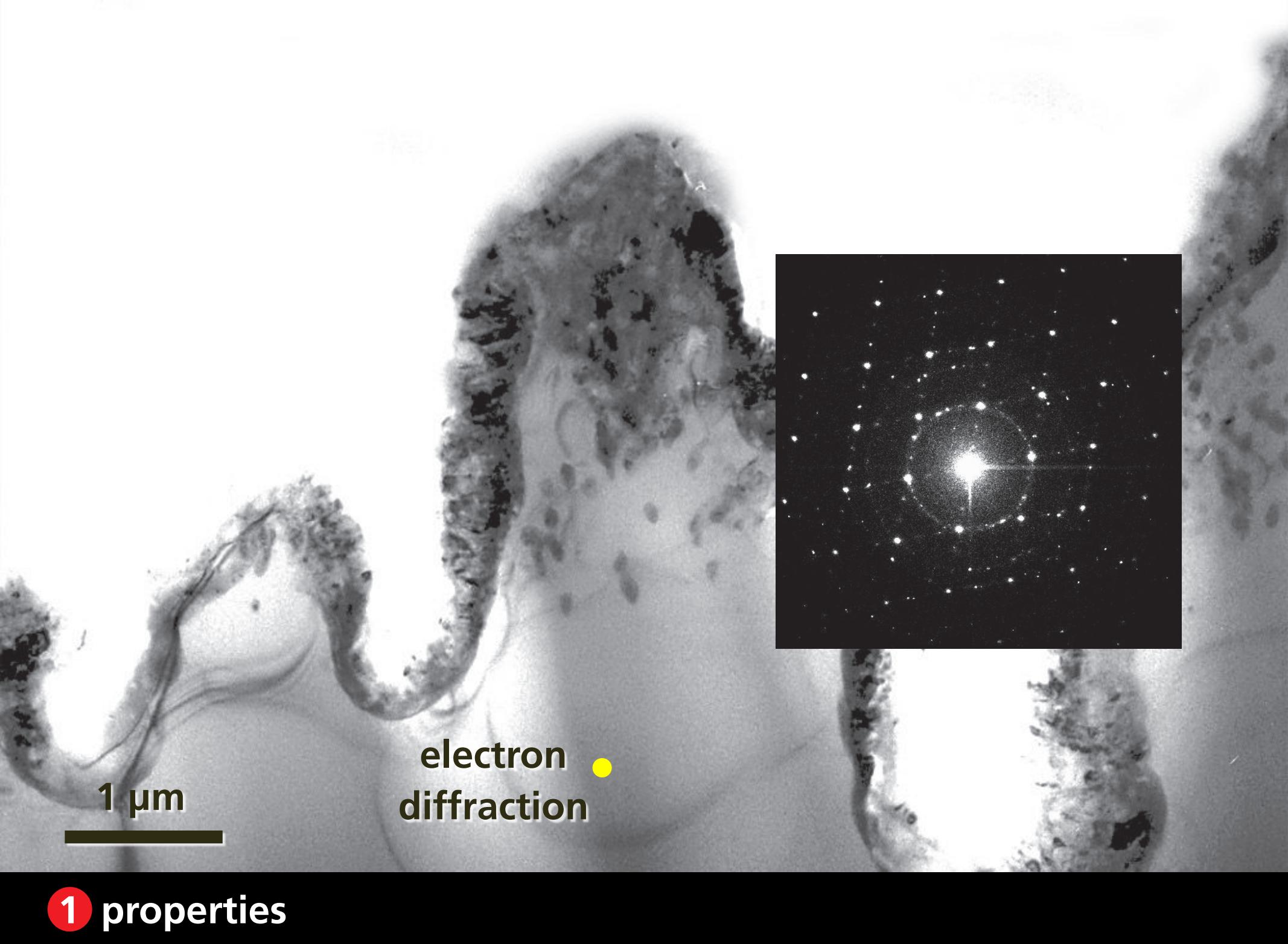
1 properties

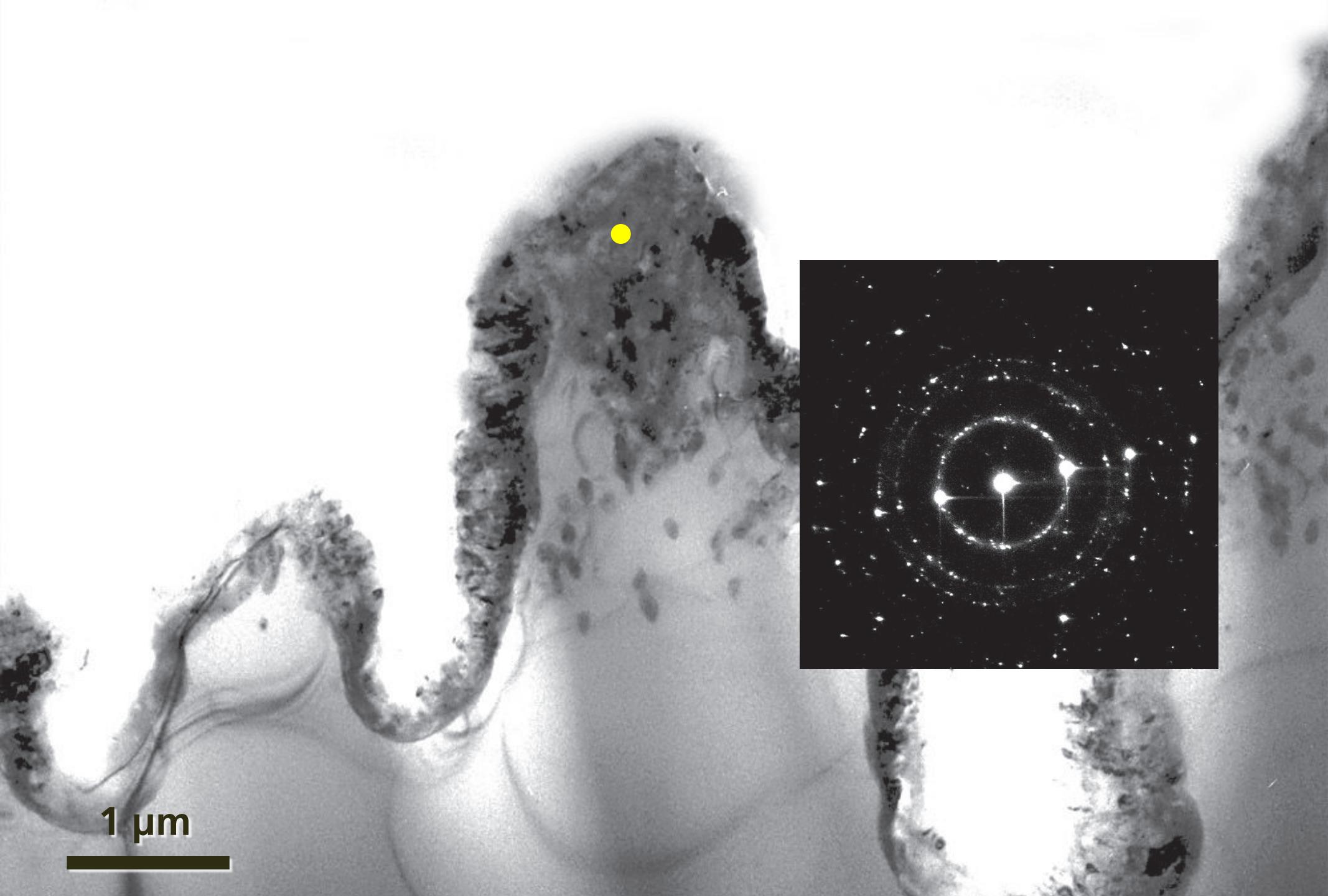


crystalline
Si core

1 μm

1 properties





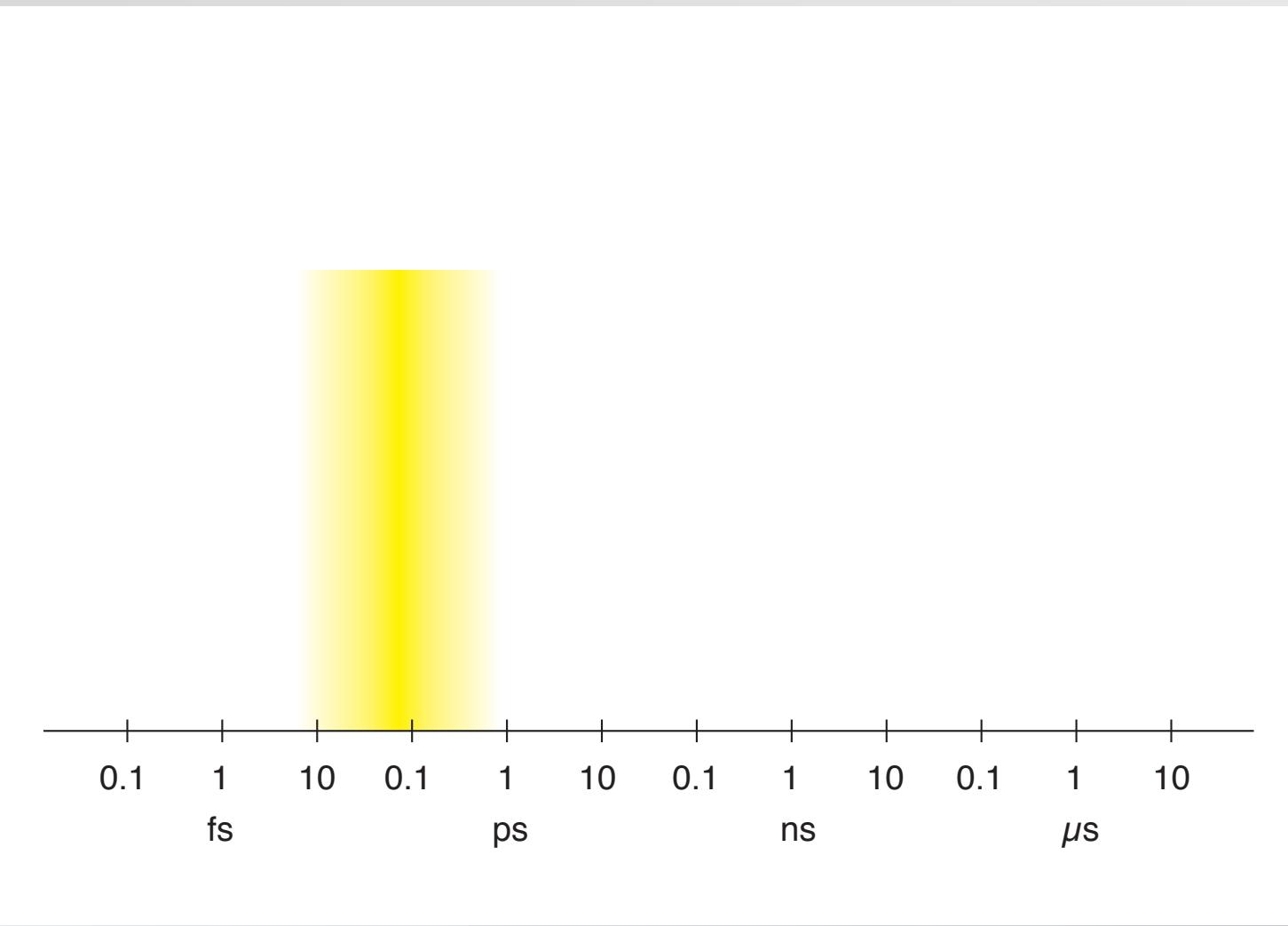
1 properties

- 300-nm disordered surface layer
- undisturbed crystalline core
- surface layer: polycrystalline Si with 1.6% sulfur

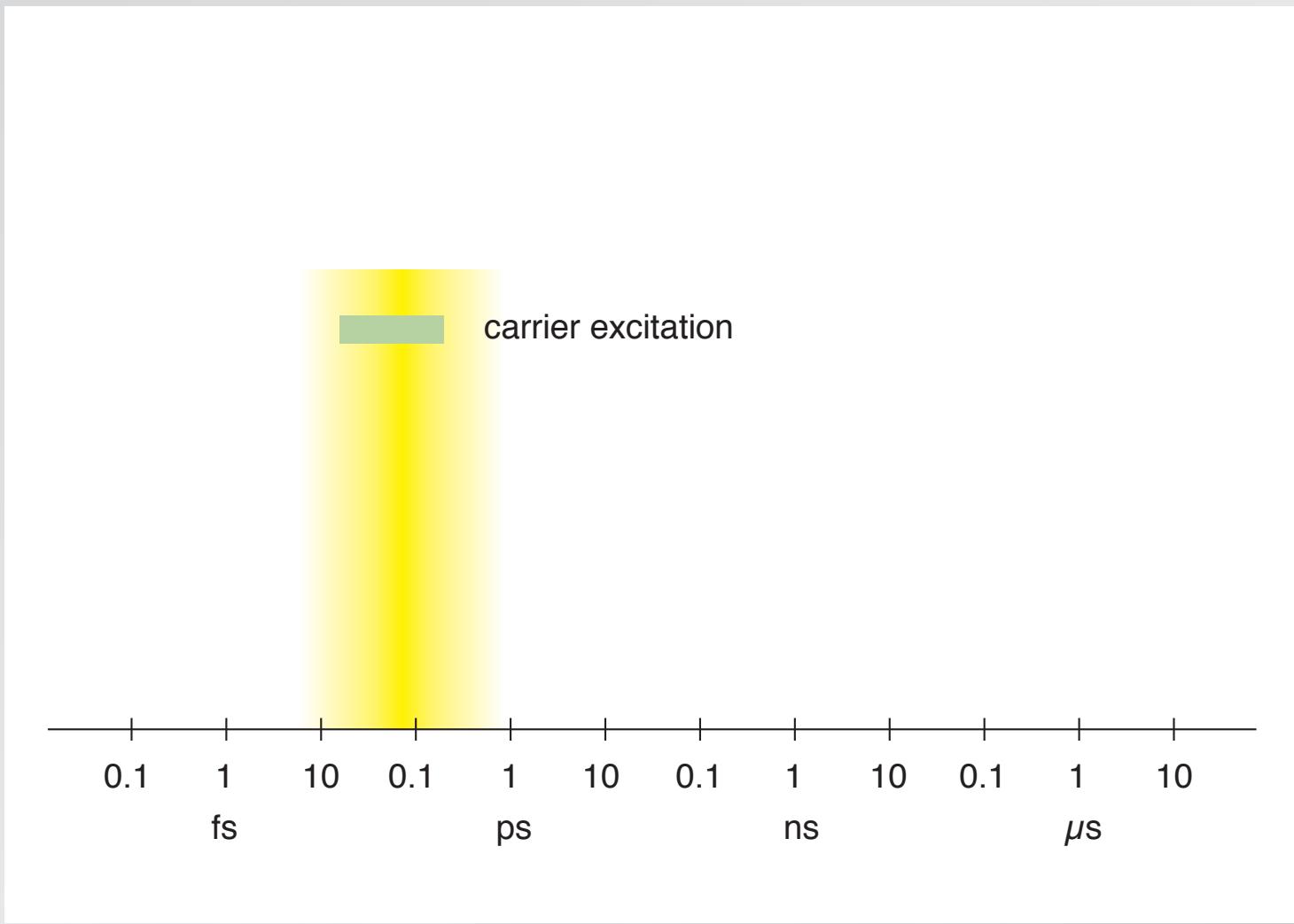
1 μm

two processes: melting and ablation

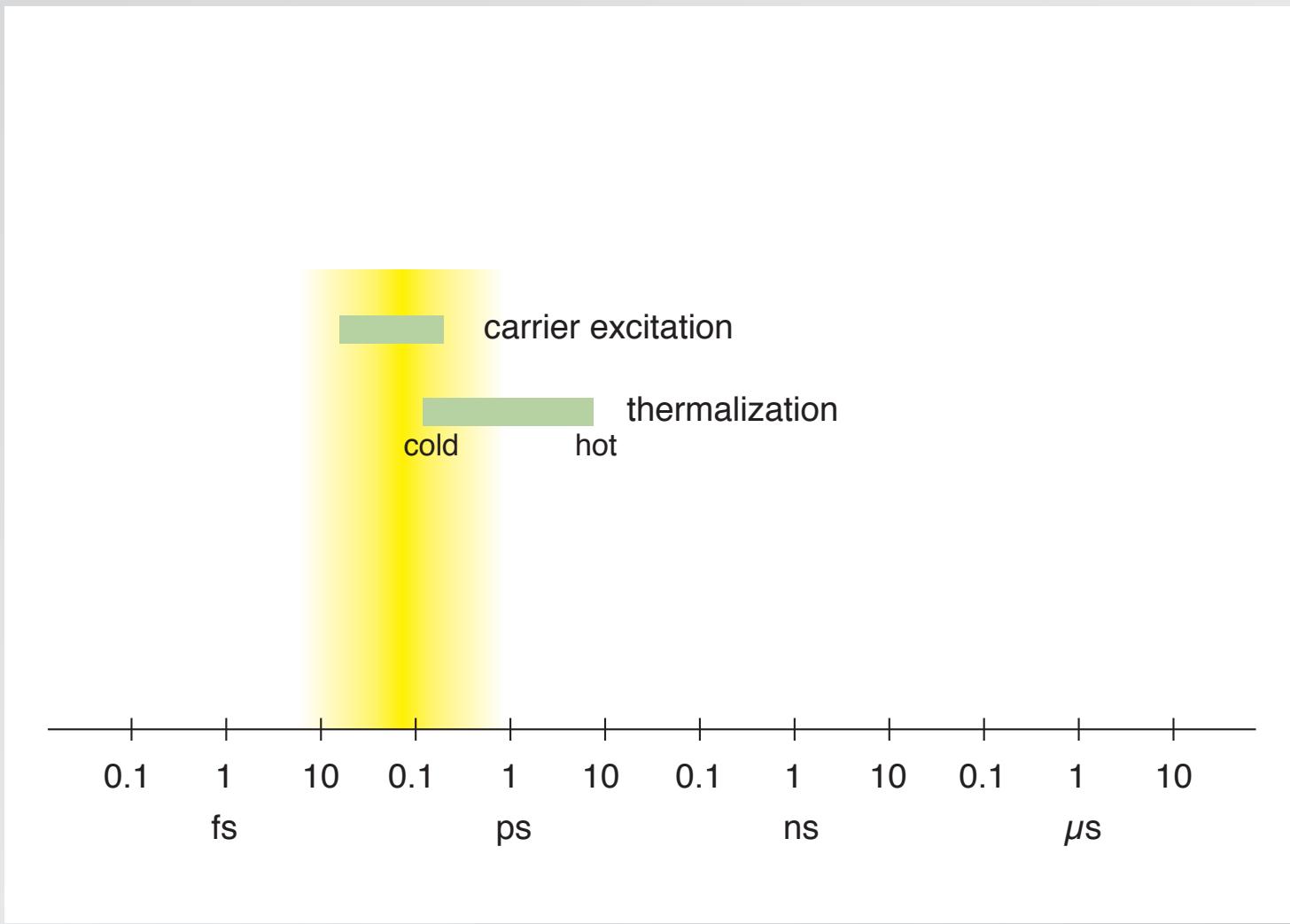
relevant time scales



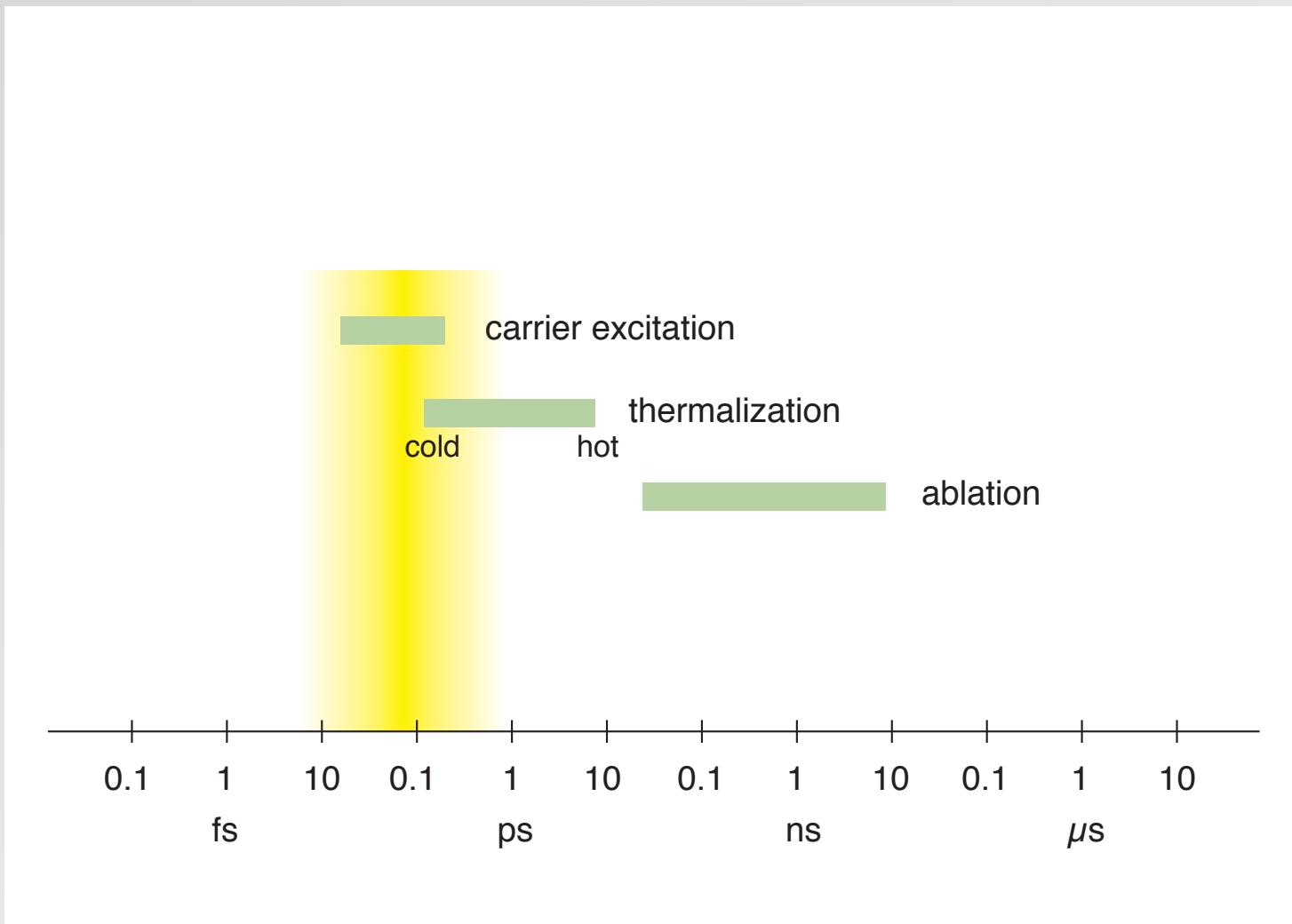
relevant time scales



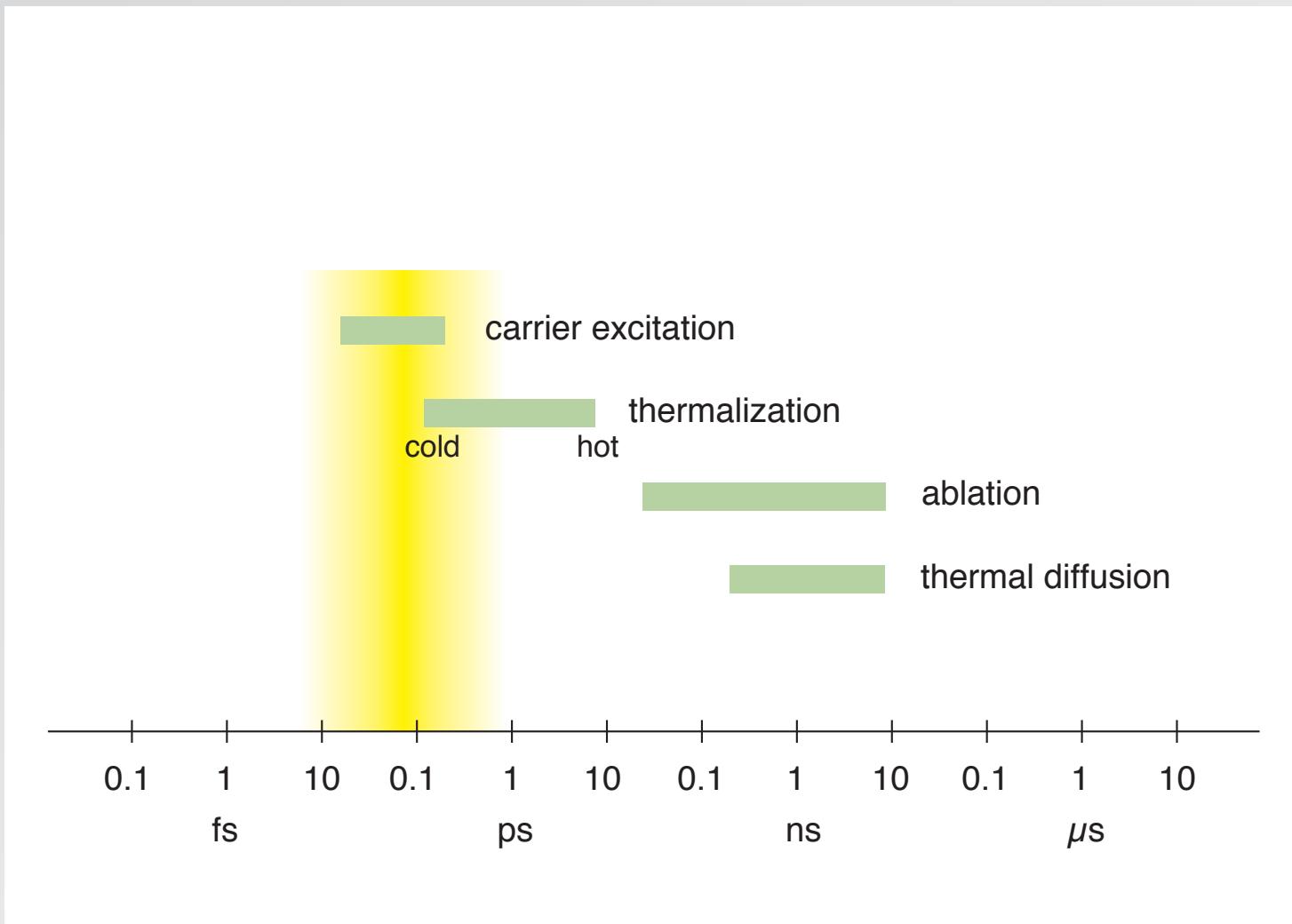
relevant time scales



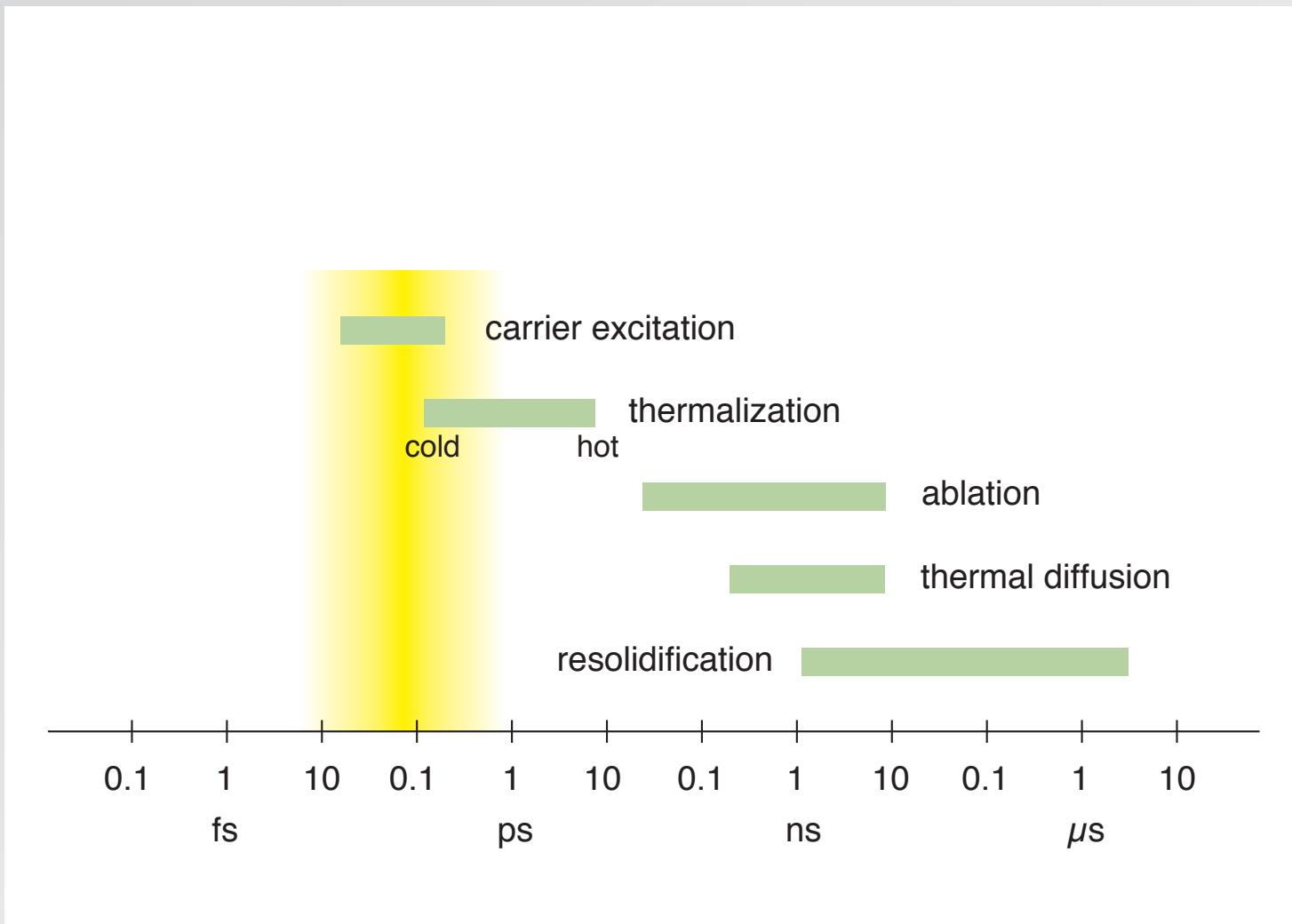
relevant time scales



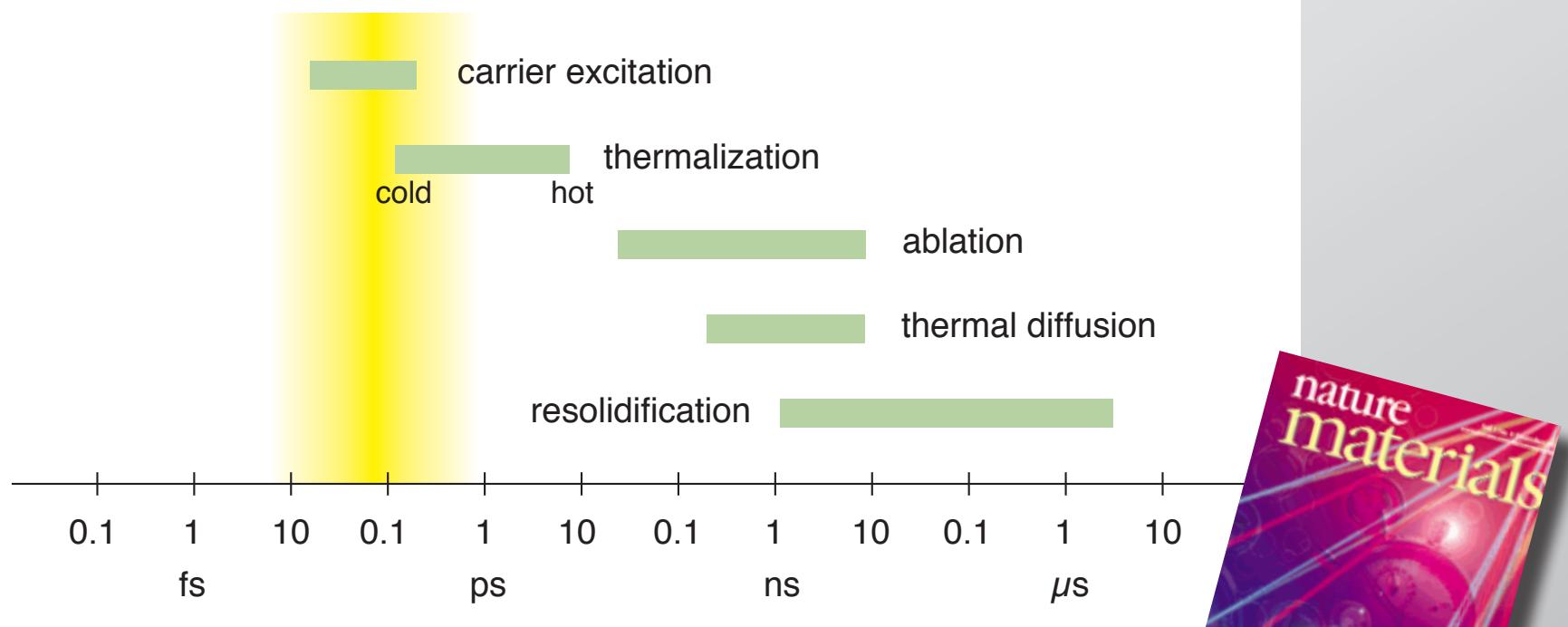
relevant time scales



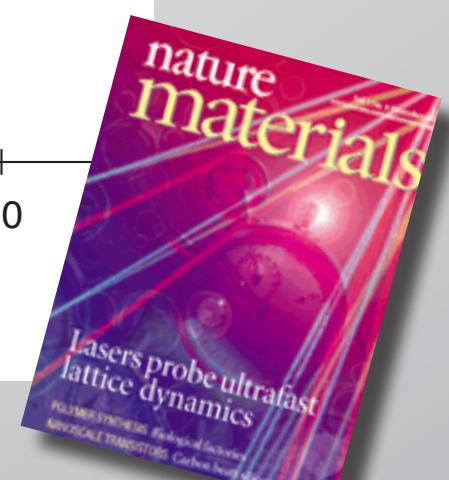
relevant time scales



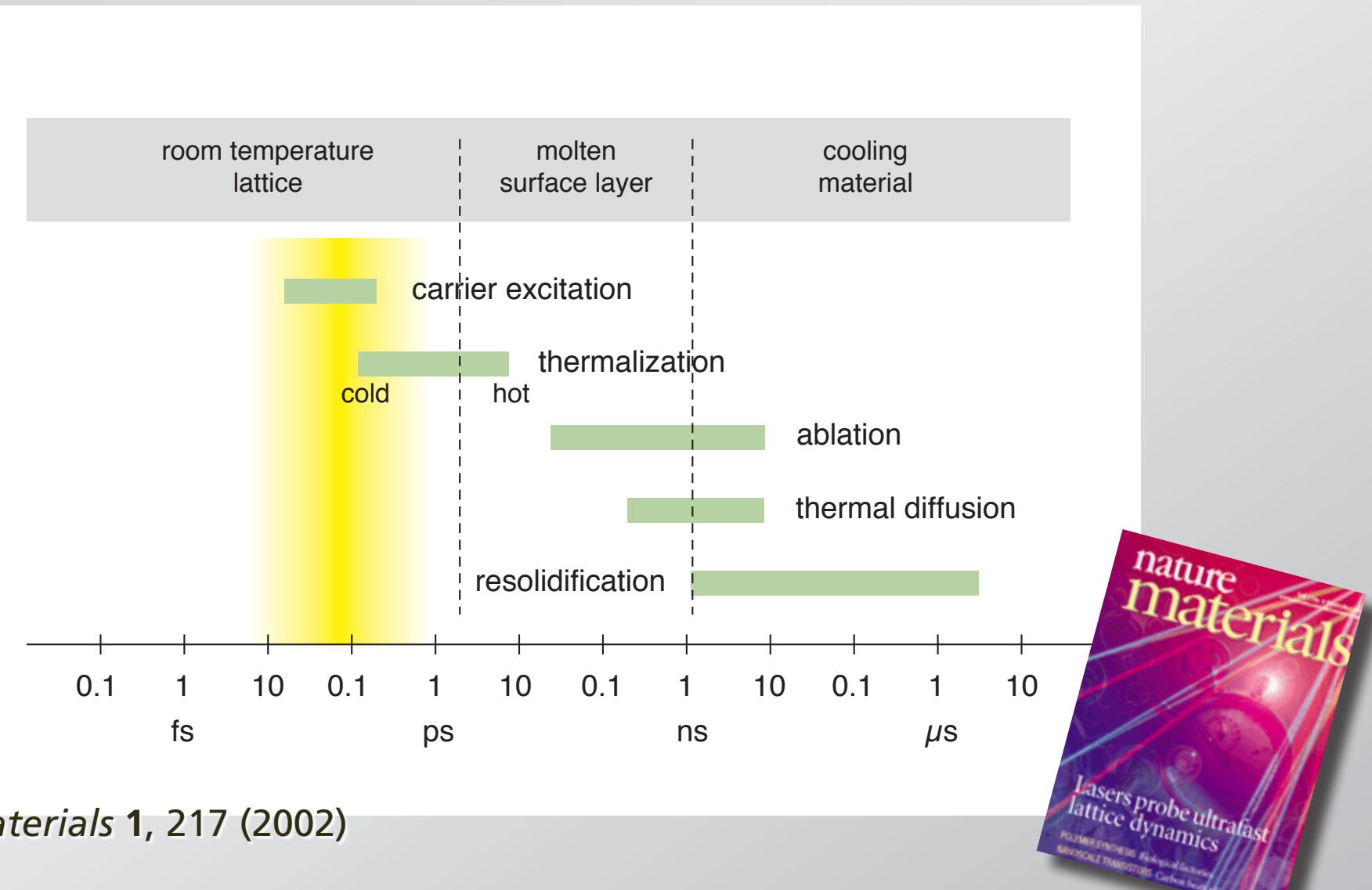
relevant time scales



Nature Materials 1, 217 (2002)

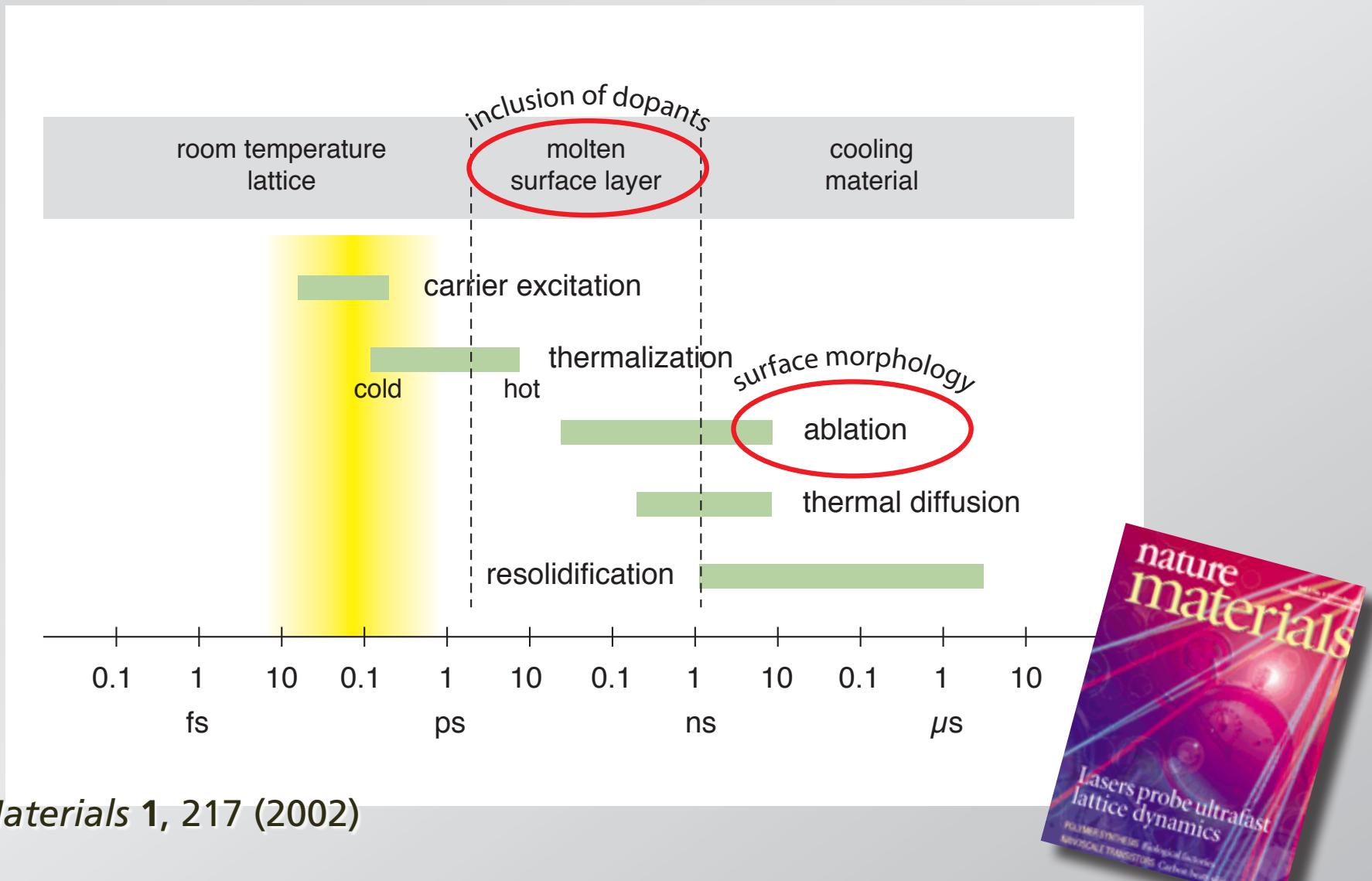


relevant time scales



Nature Materials 1, 217 (2002)

relevant time scales



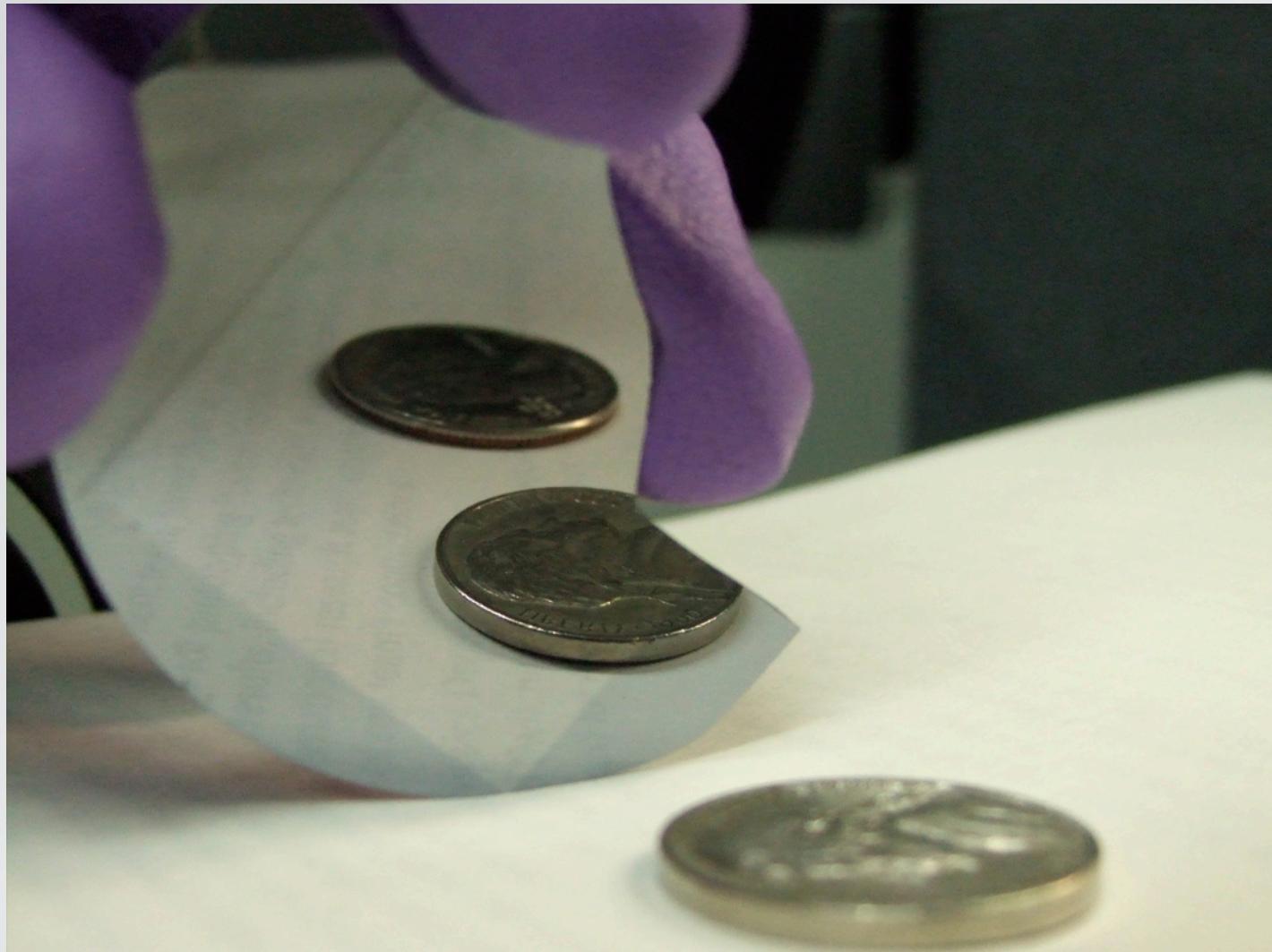
Nature Materials 1, 217 (2002)

different thresholds:

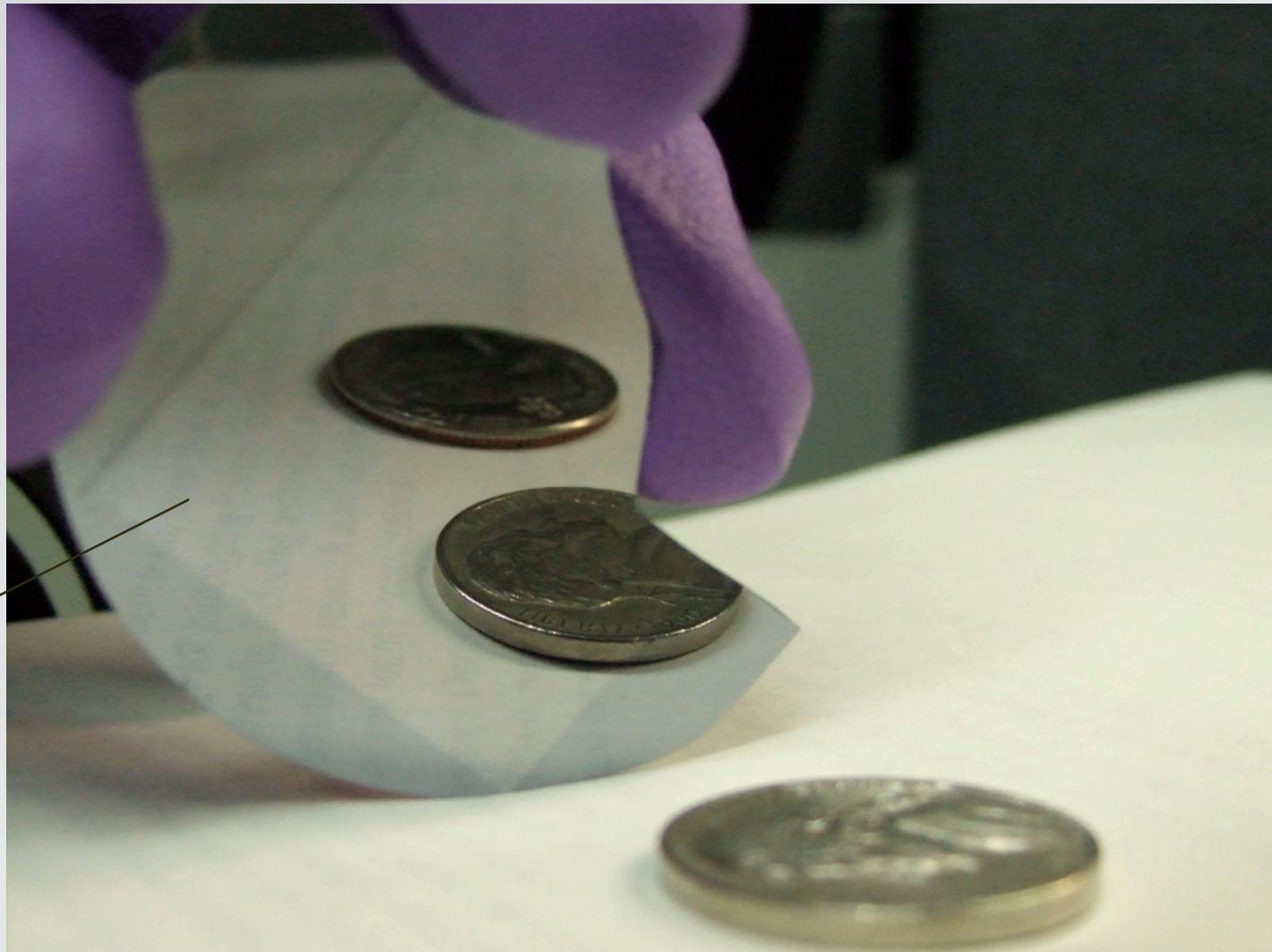
melting: 1.5 kJ/m^2

ablation: 3.1 kJ/m^2

decouple ablation from melting

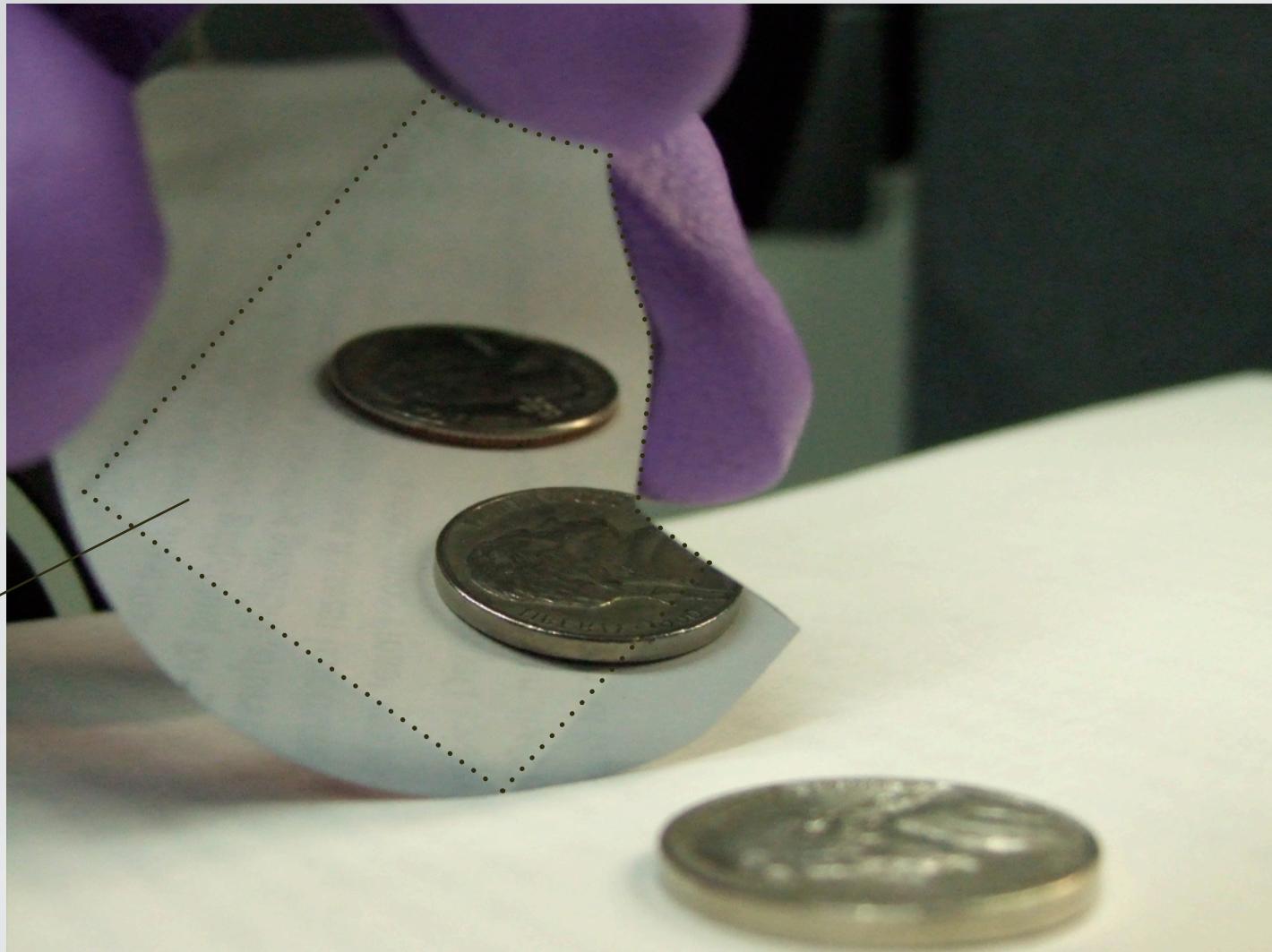


decouple ablation from melting



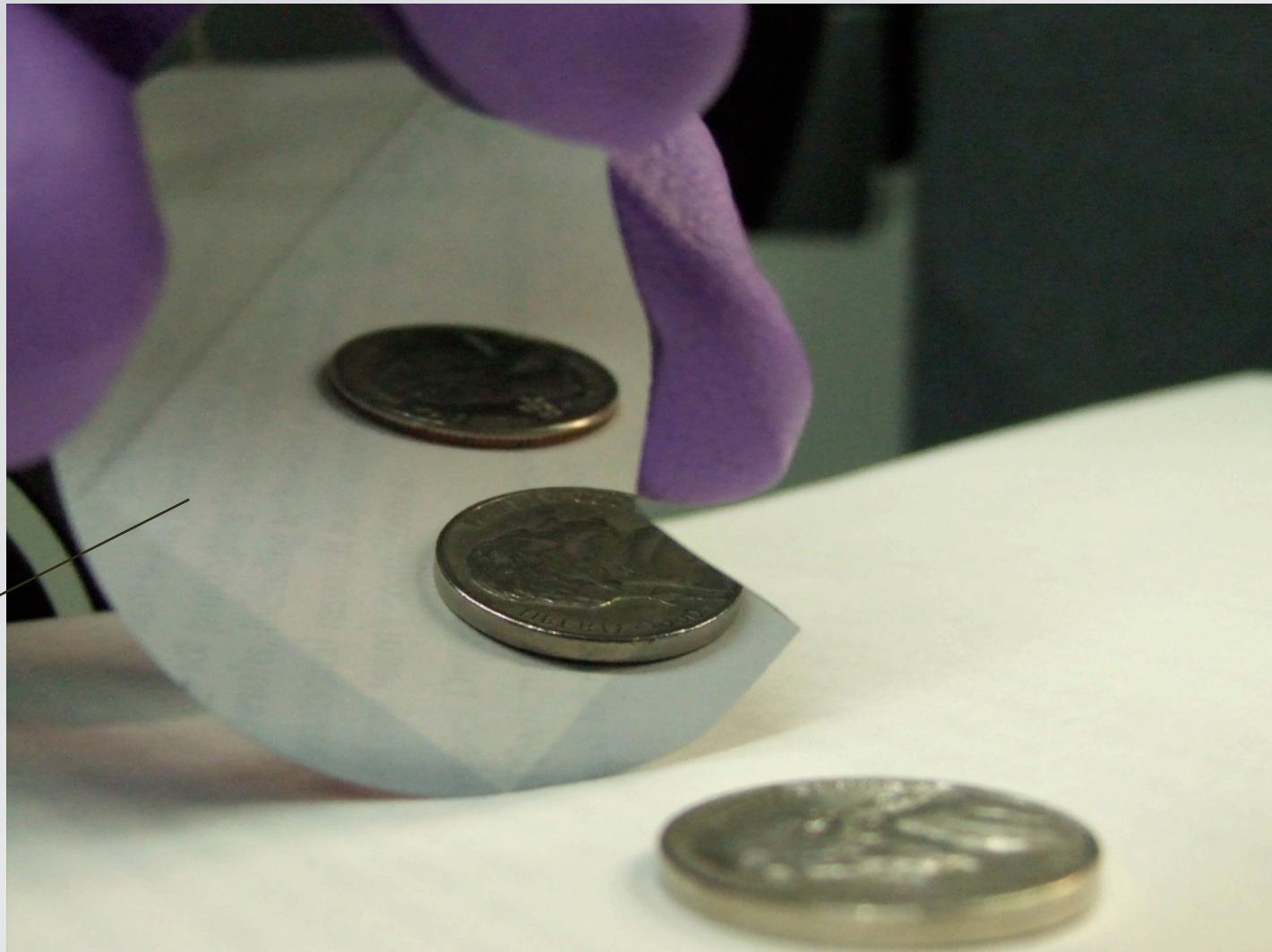
1 properties

decouple ablation from melting



1 properties

decouple ablation from melting

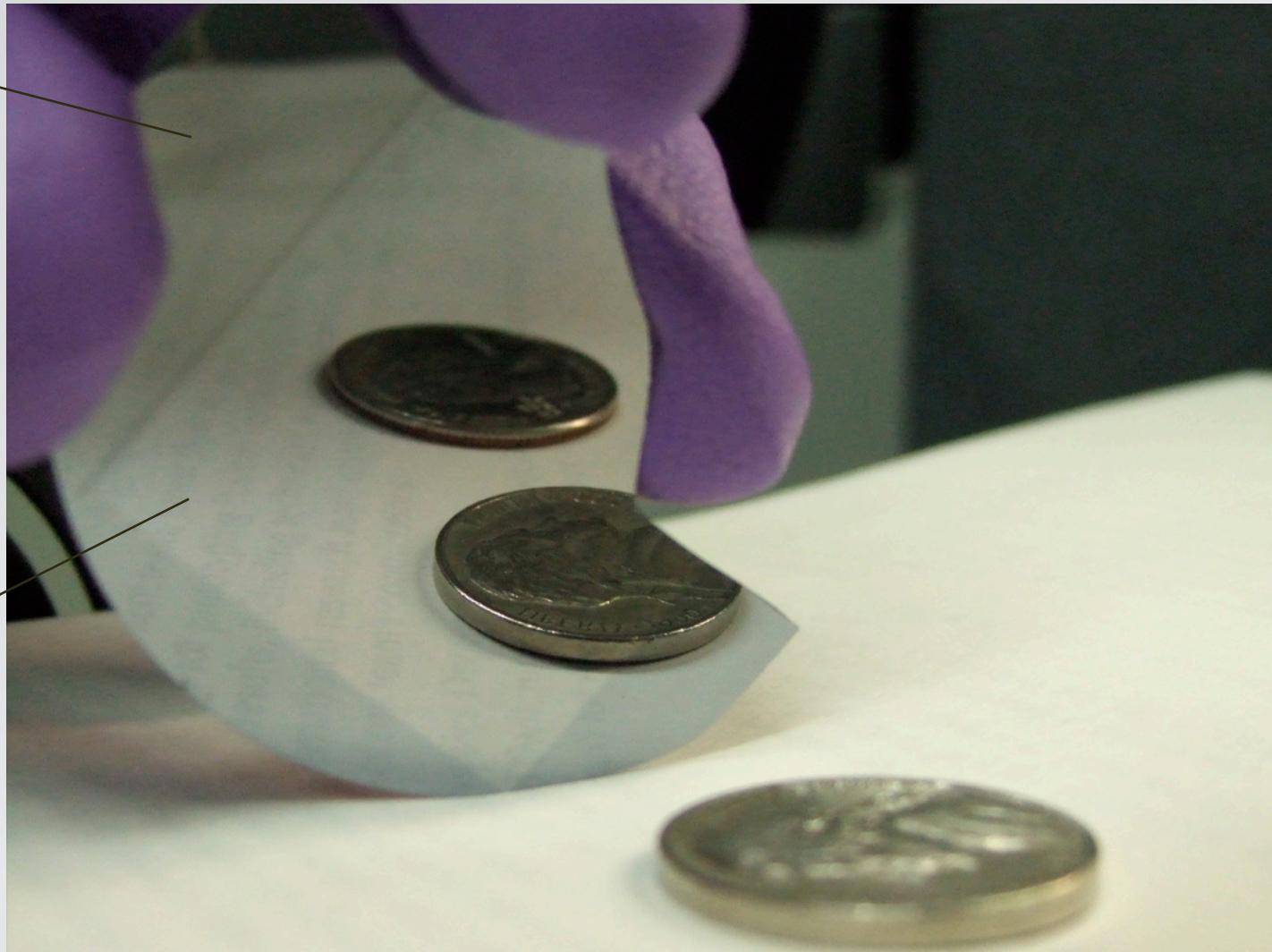


1 properties

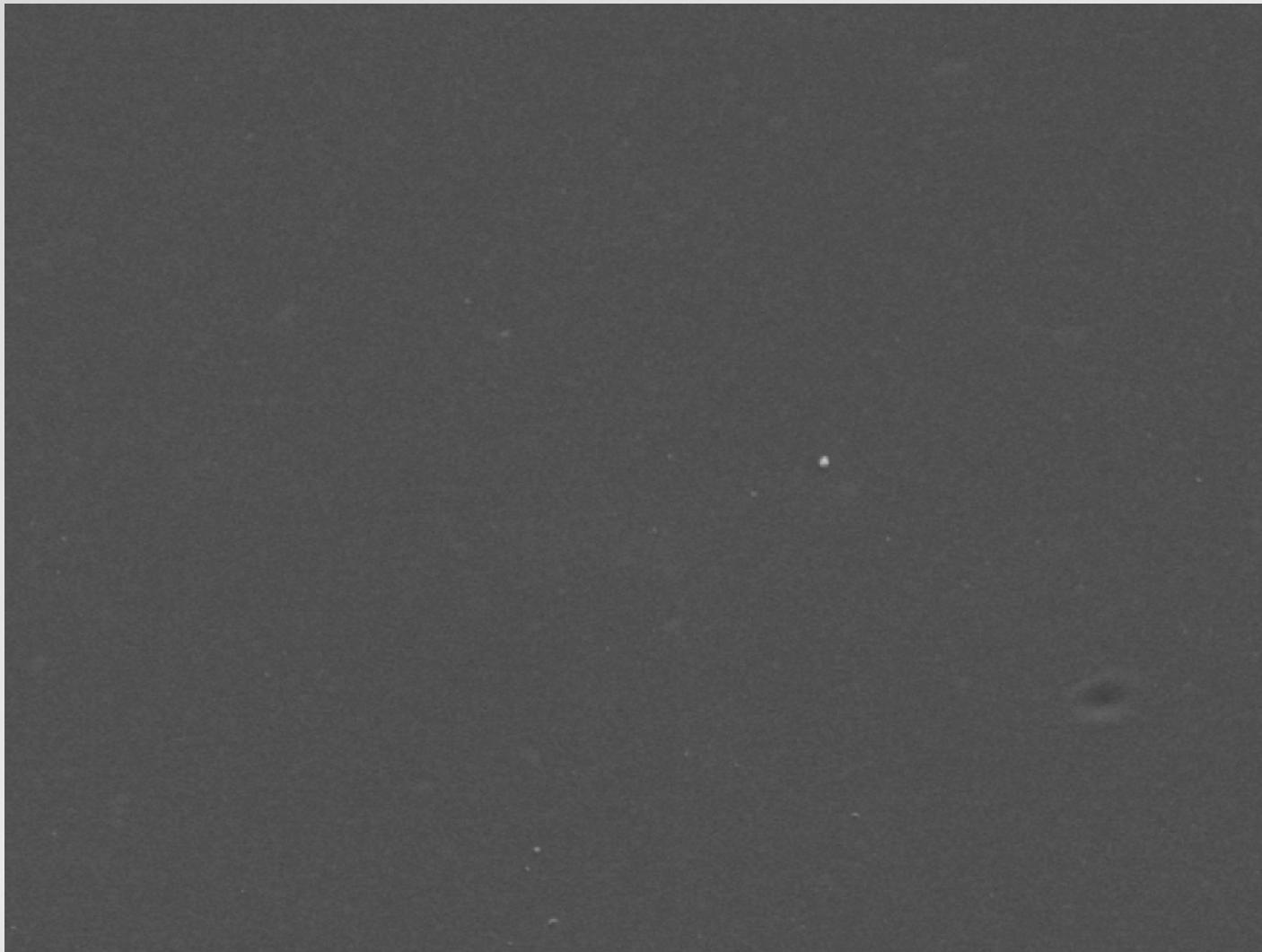
decouple ablation from melting

undoped

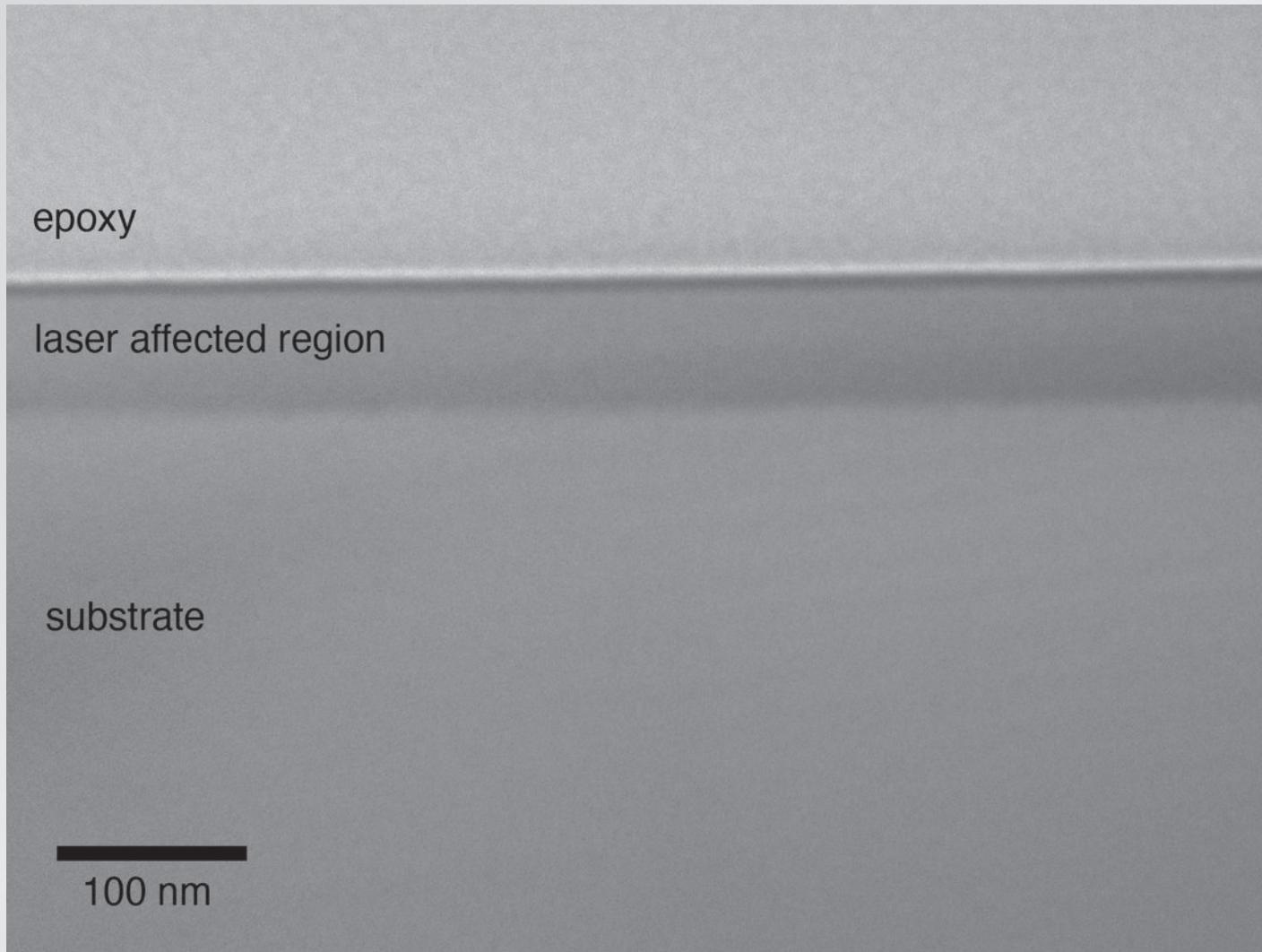
doped



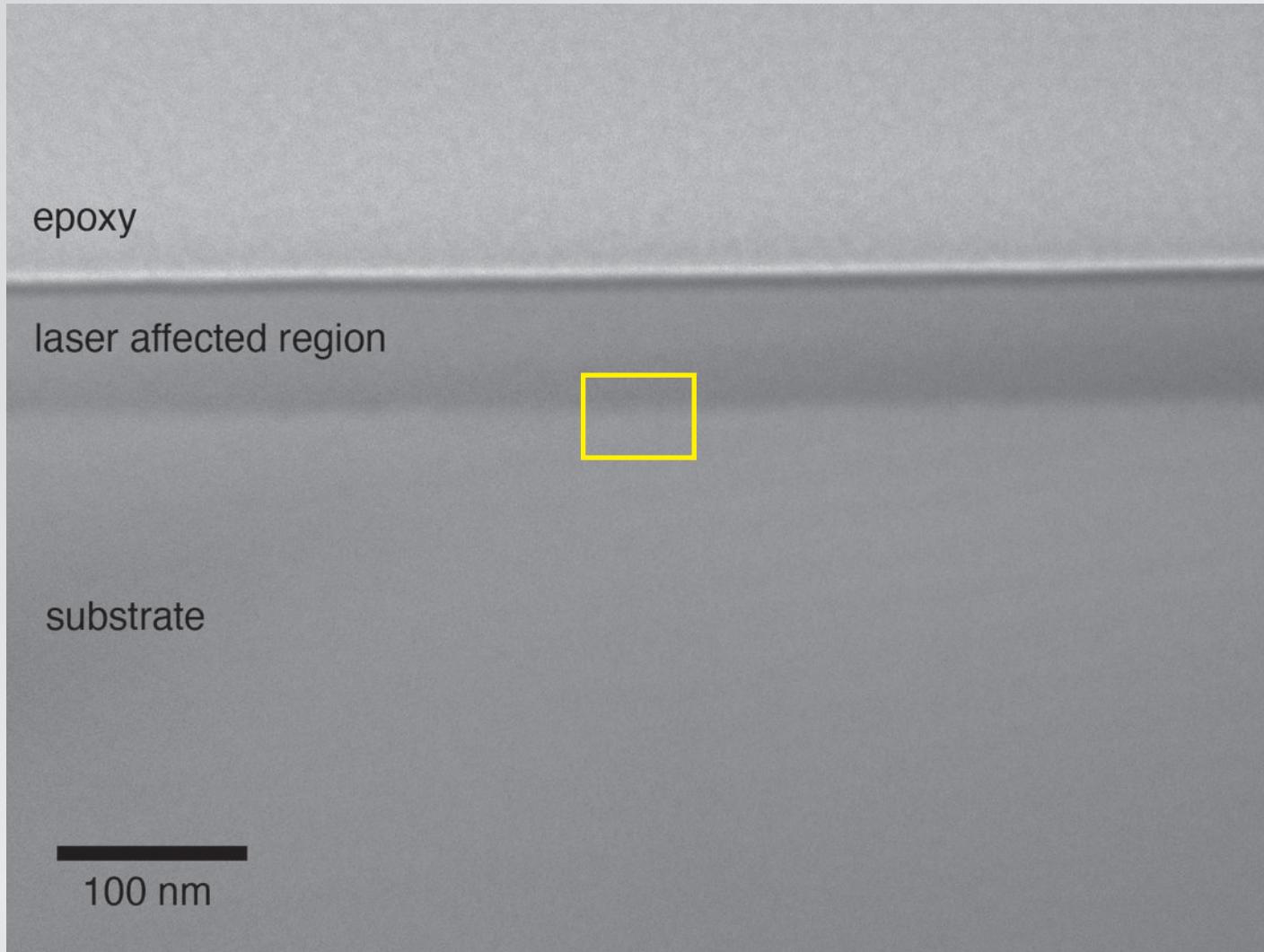
decouple ablation from melting



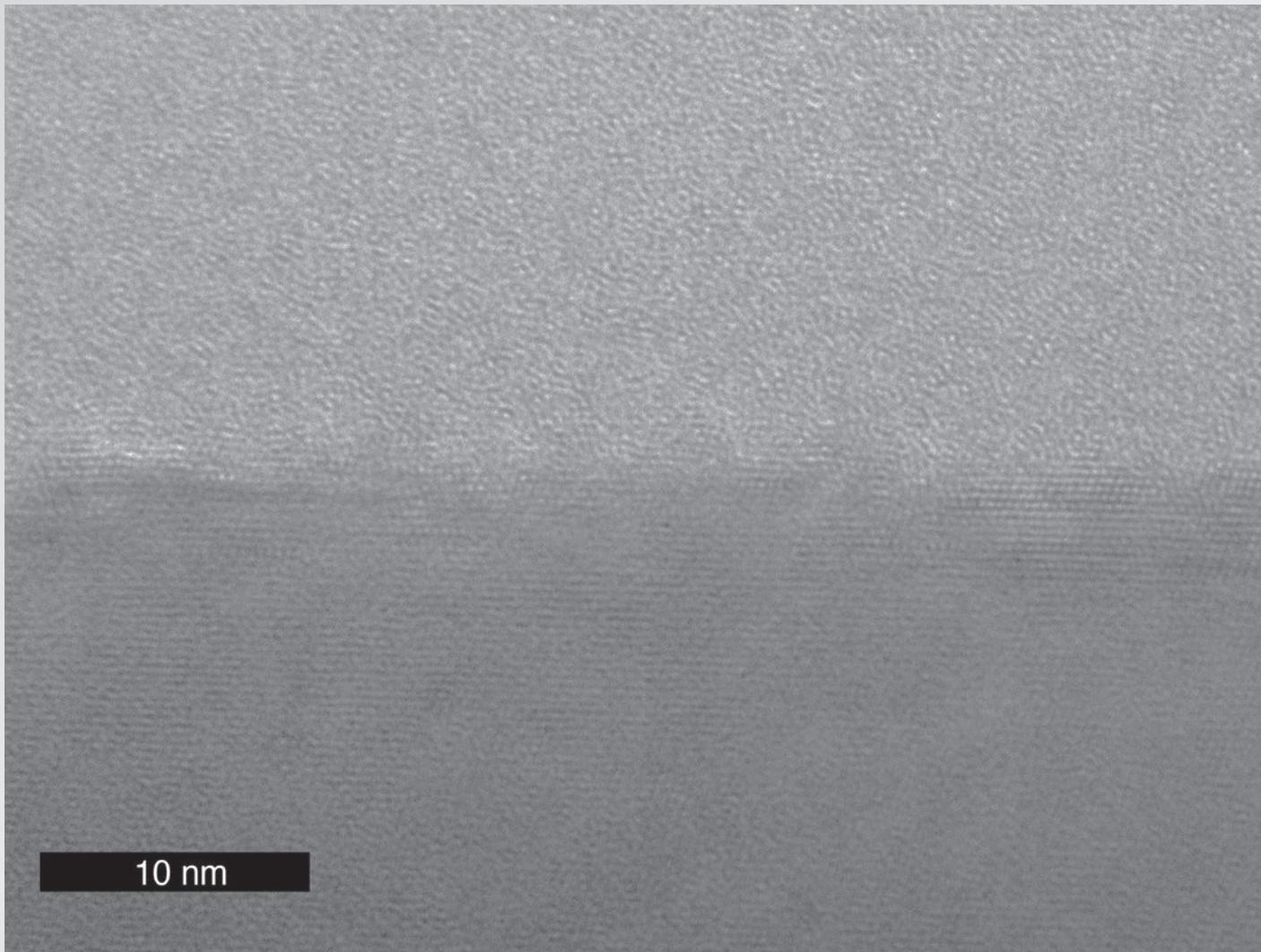
decouple ablation from melting



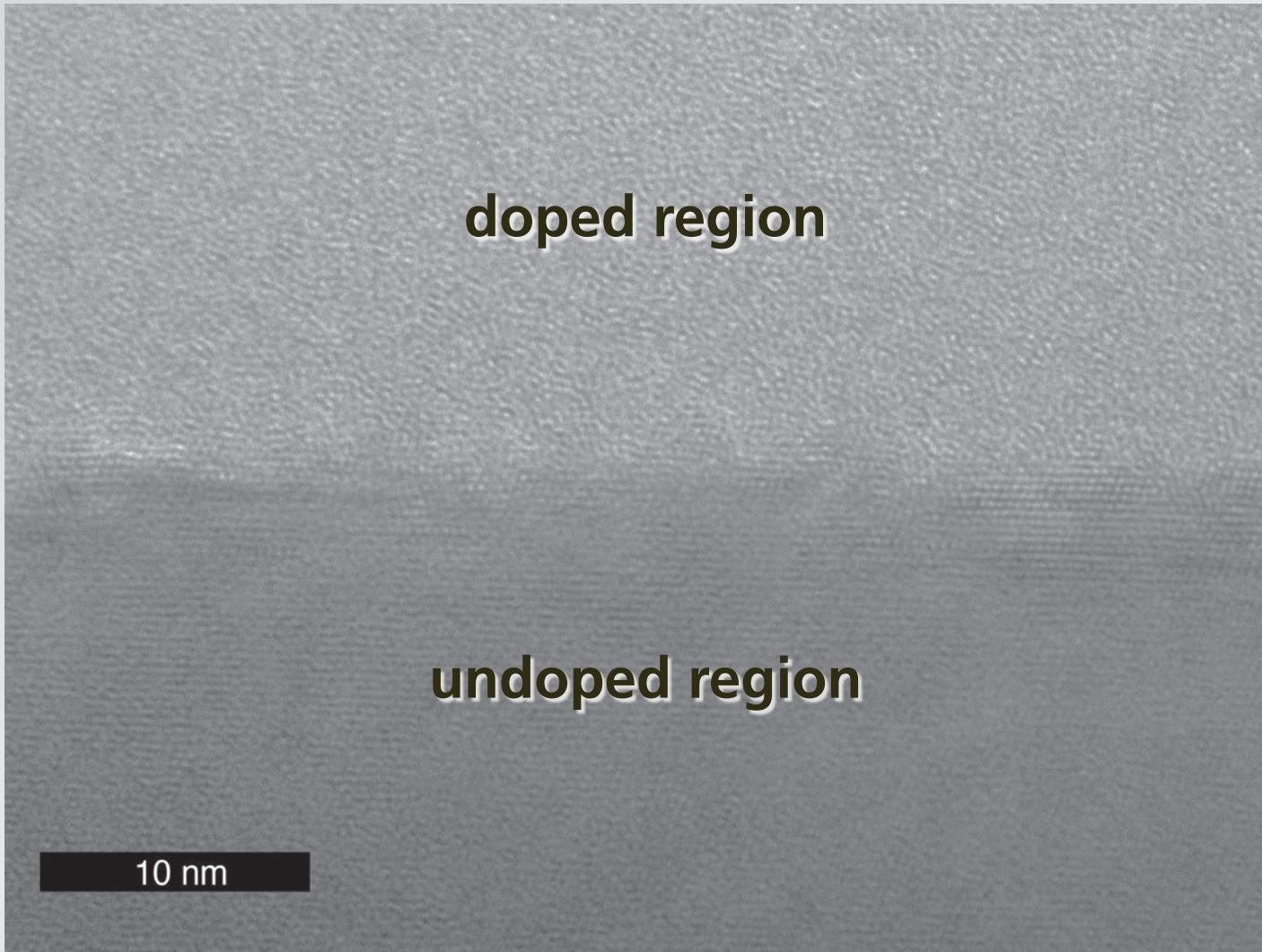
decouple ablation from melting



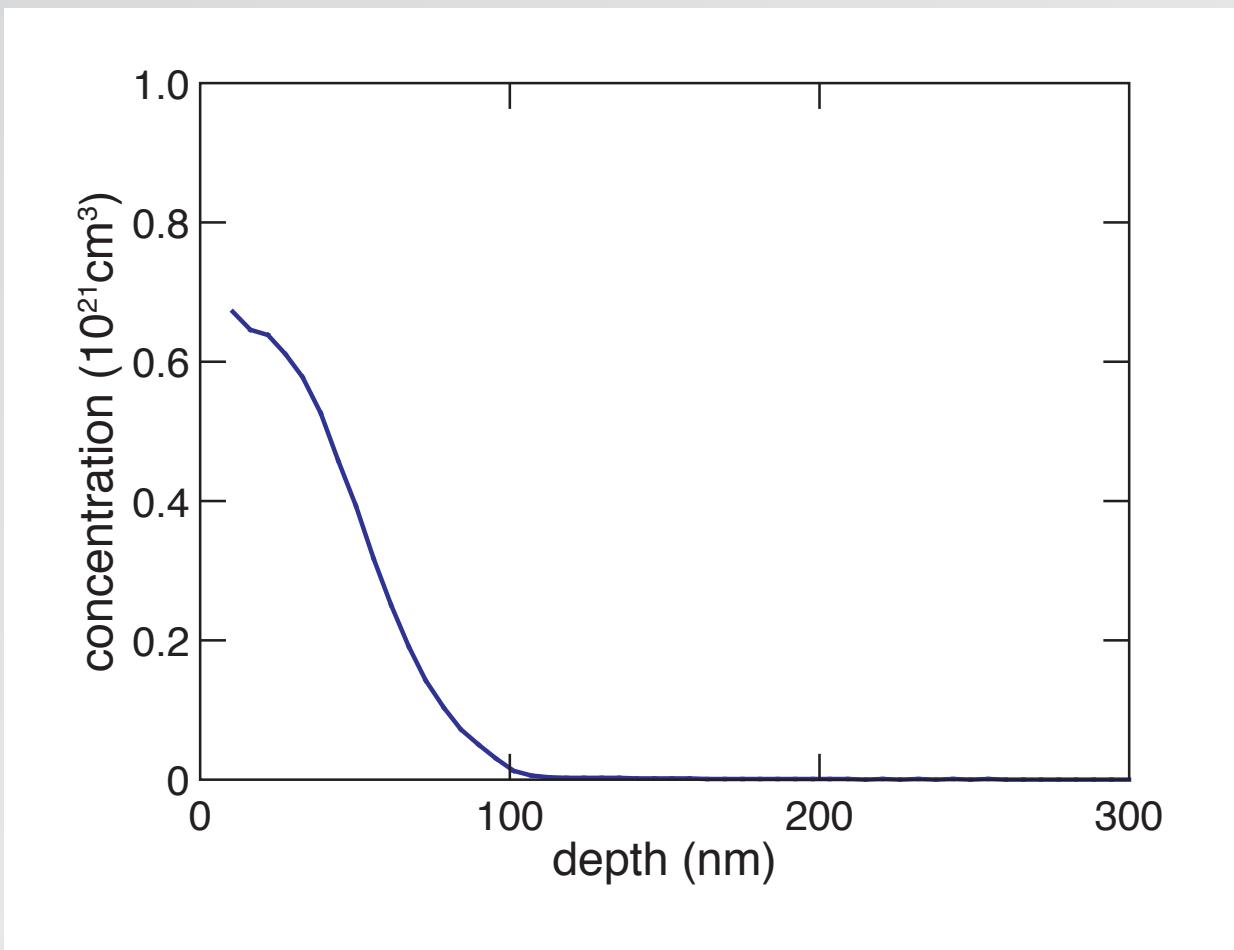
decouple ablation from melting



decouple ablation from melting

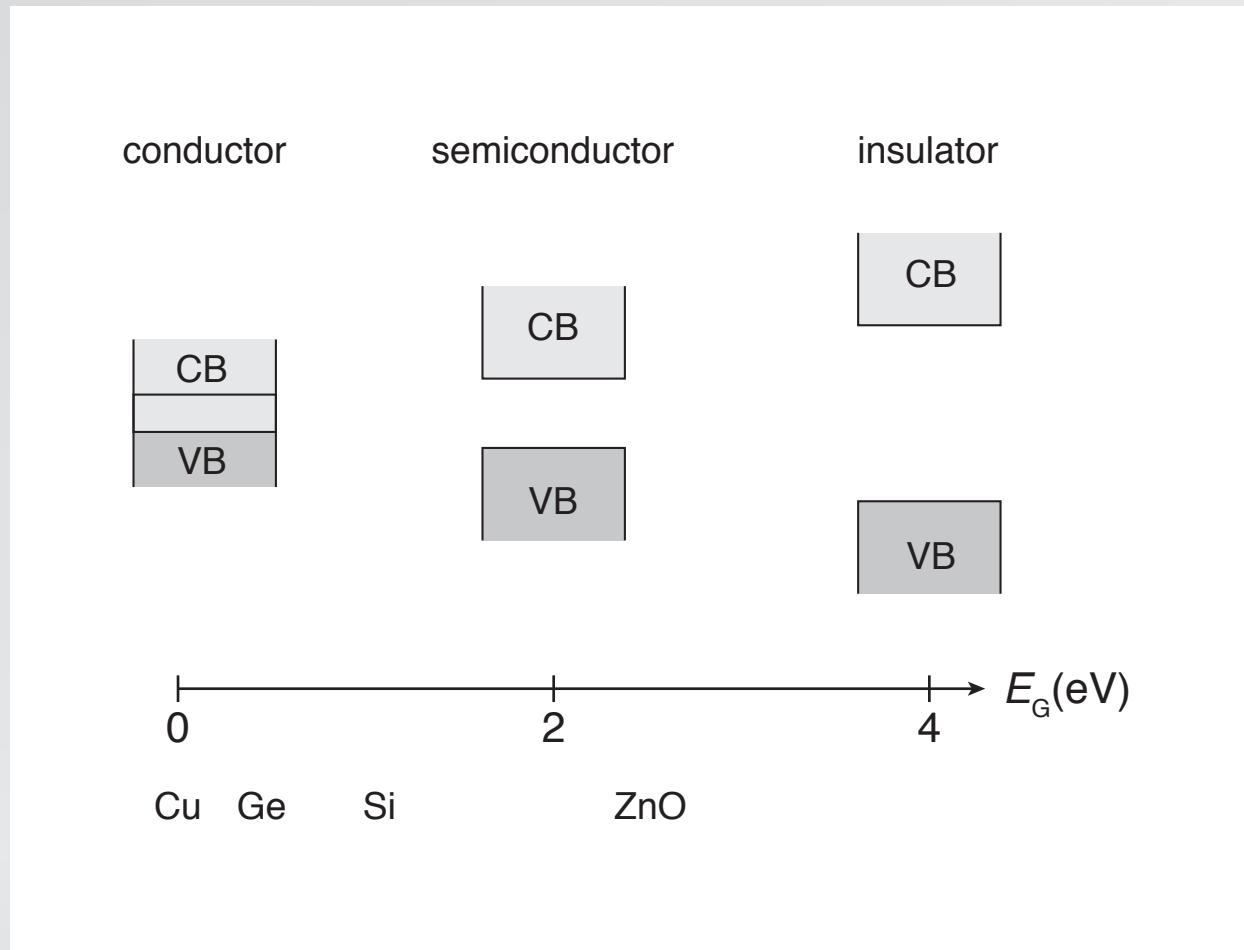


secondary ion mass spectrometry



Things to keep in mind

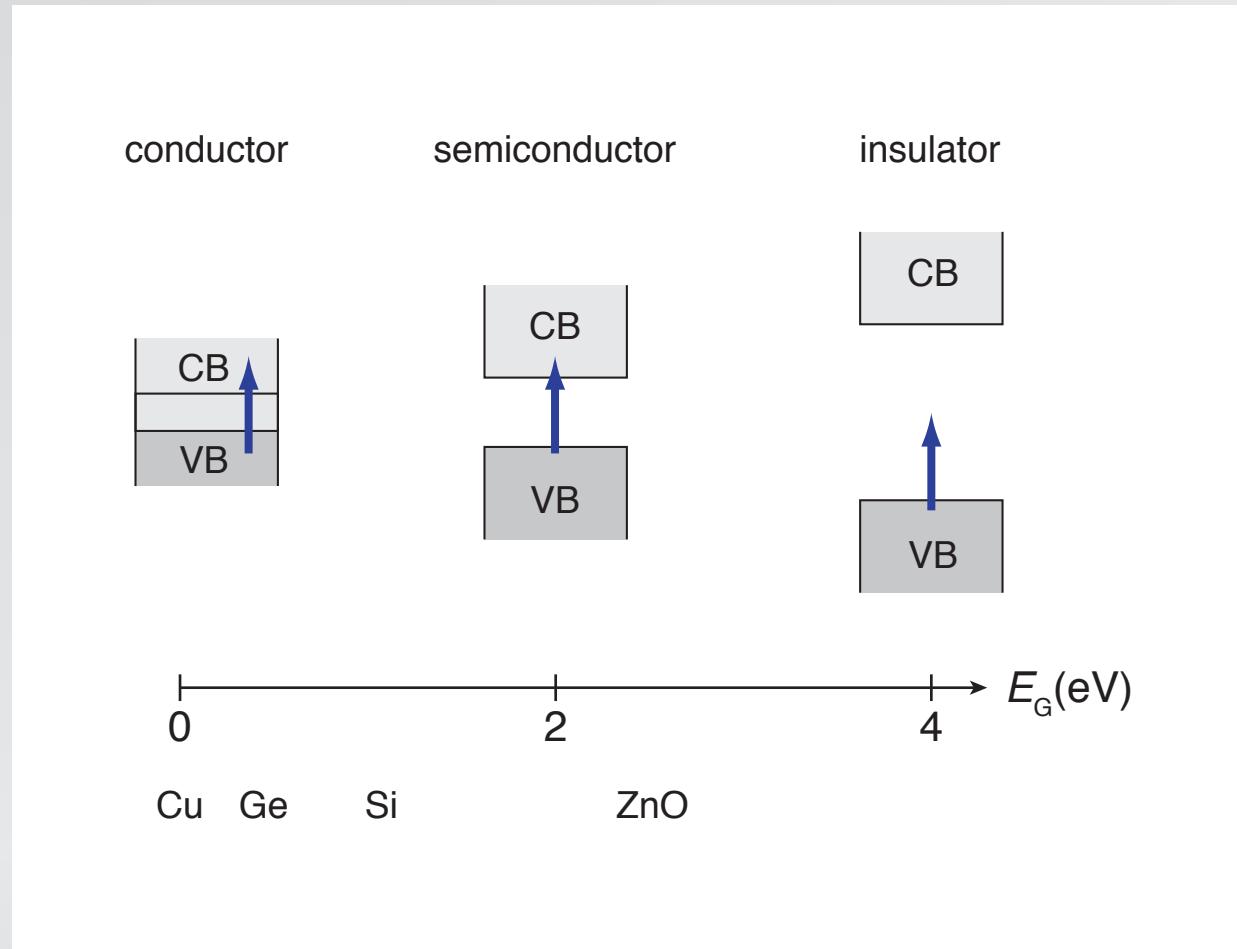
- near unit absorption extending into IR
- surface structure due to ablation
- hyperdoping due to rapid melting and resolidification
- can decouple both processes



1 properties

2 intermediate band

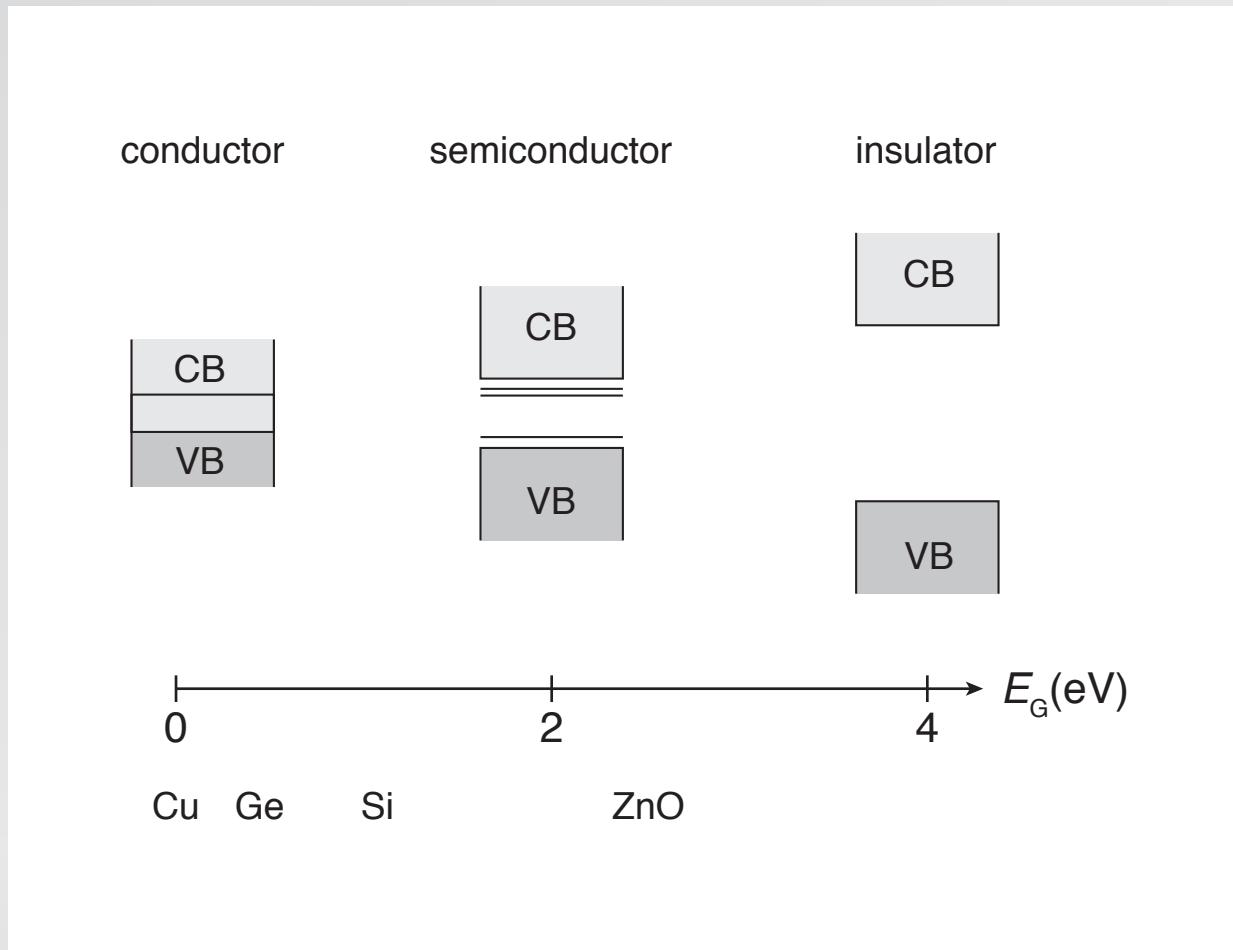
gap determines optical and electronic properties



1 properties

2 intermediate band

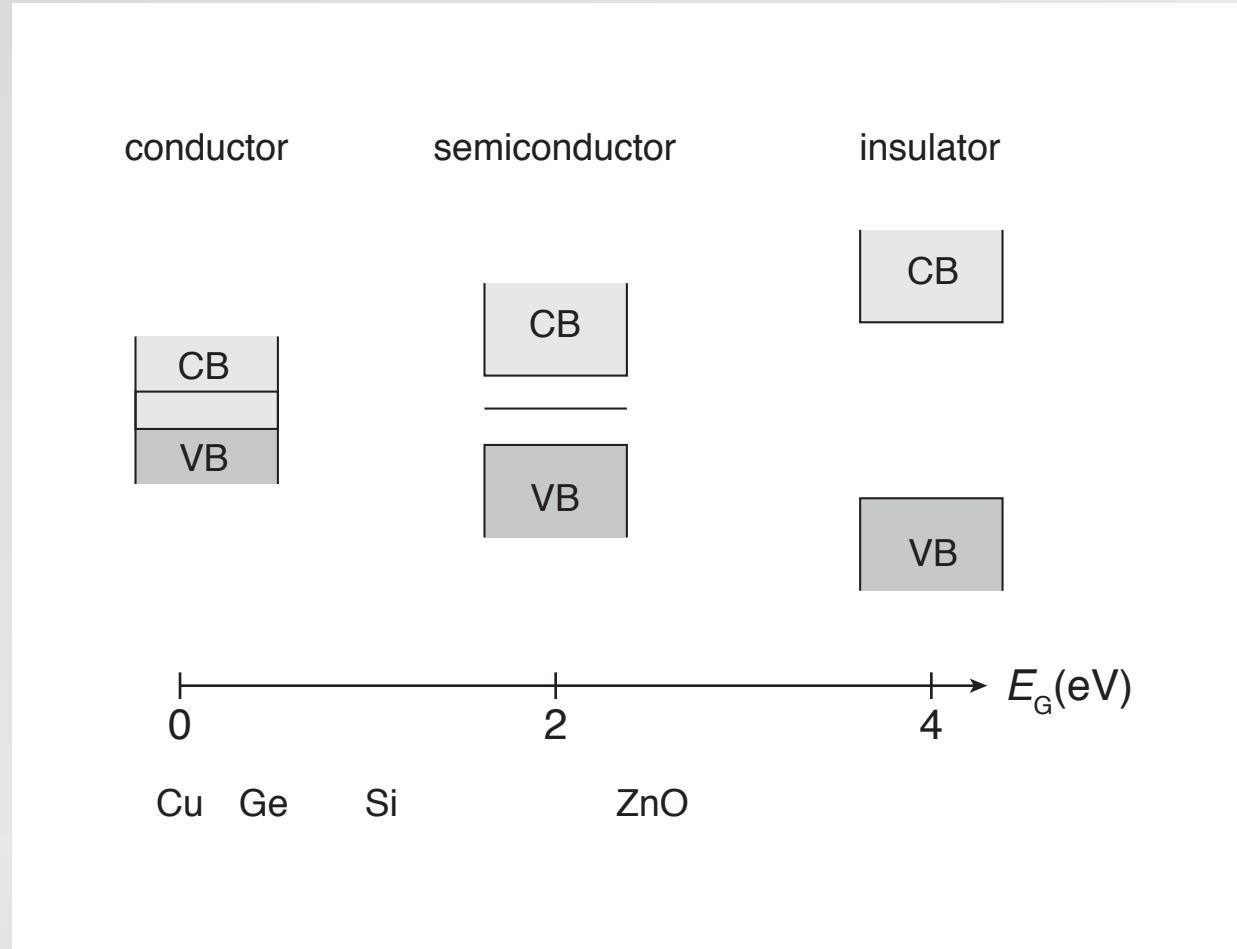
shallow-level dopants control electronic properties



1 properties

2 intermediate band

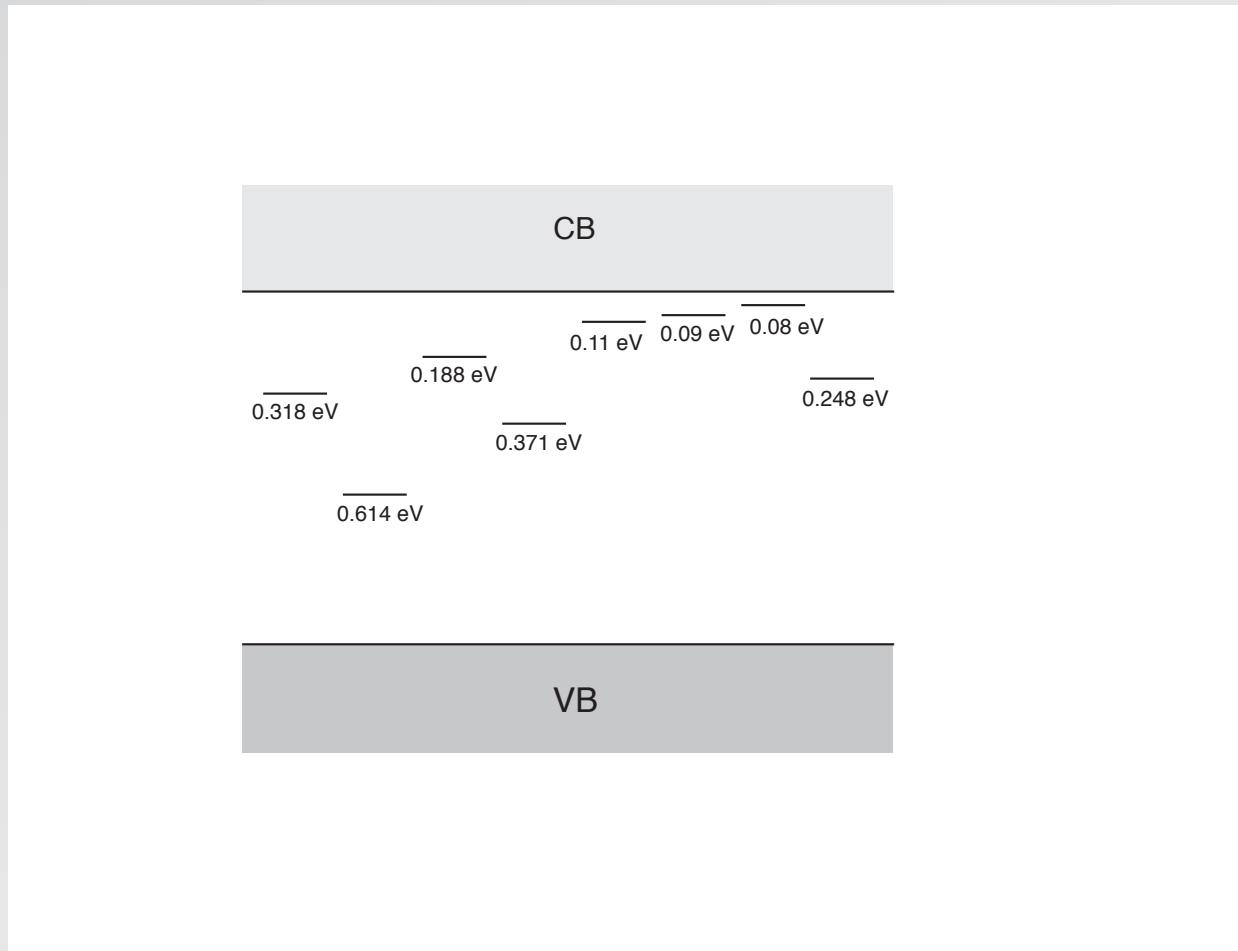
deep-level dopants typically avoided



1 properties

2 intermediate band

1 part in 10^6 sulfur introduces donor states in gap

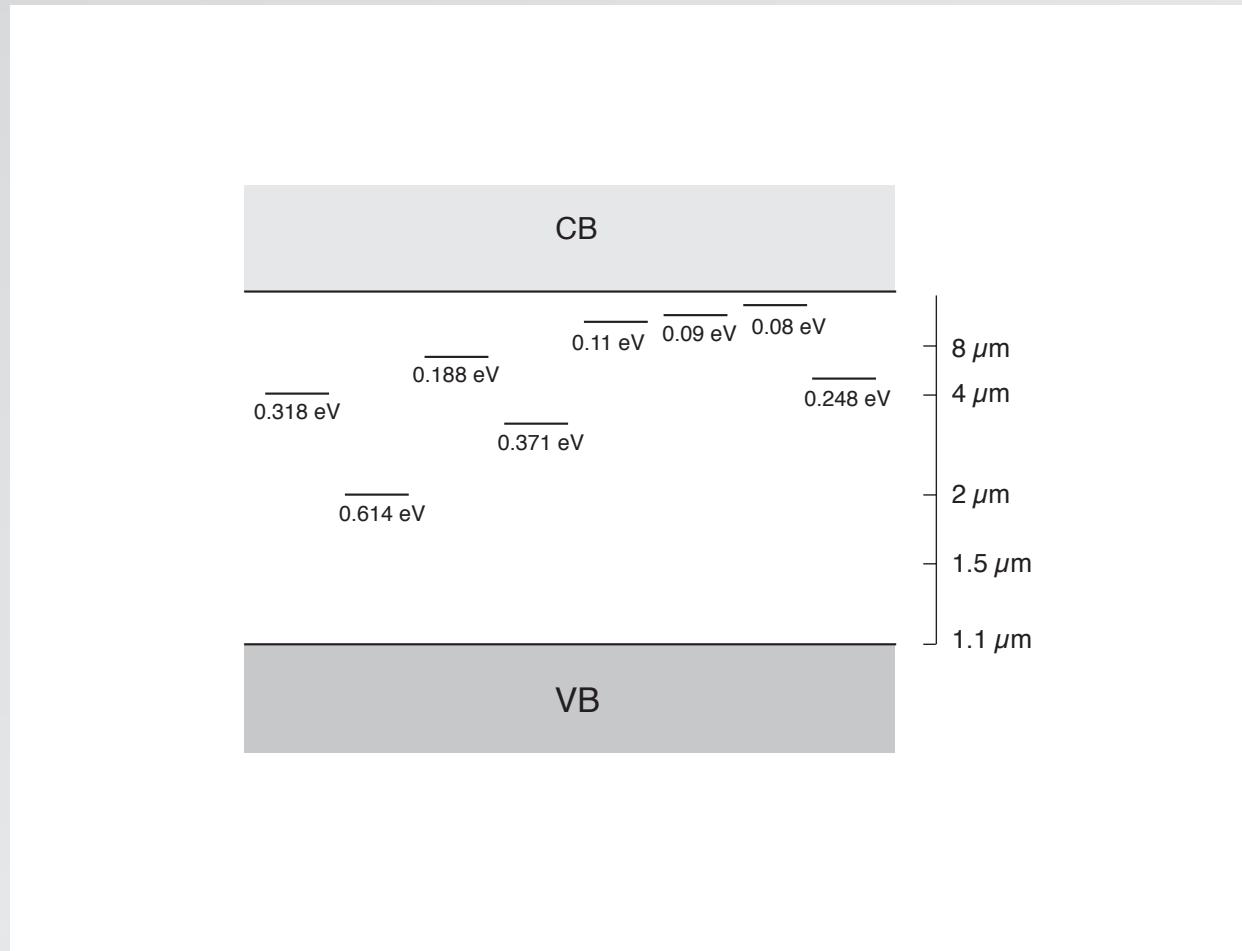


Janzén *et al.*, Phys. Rev. B 29, 1907 (1984)

1 properties

2 intermediate band

1 part in 10^6 sulfur introduces donor states in gap

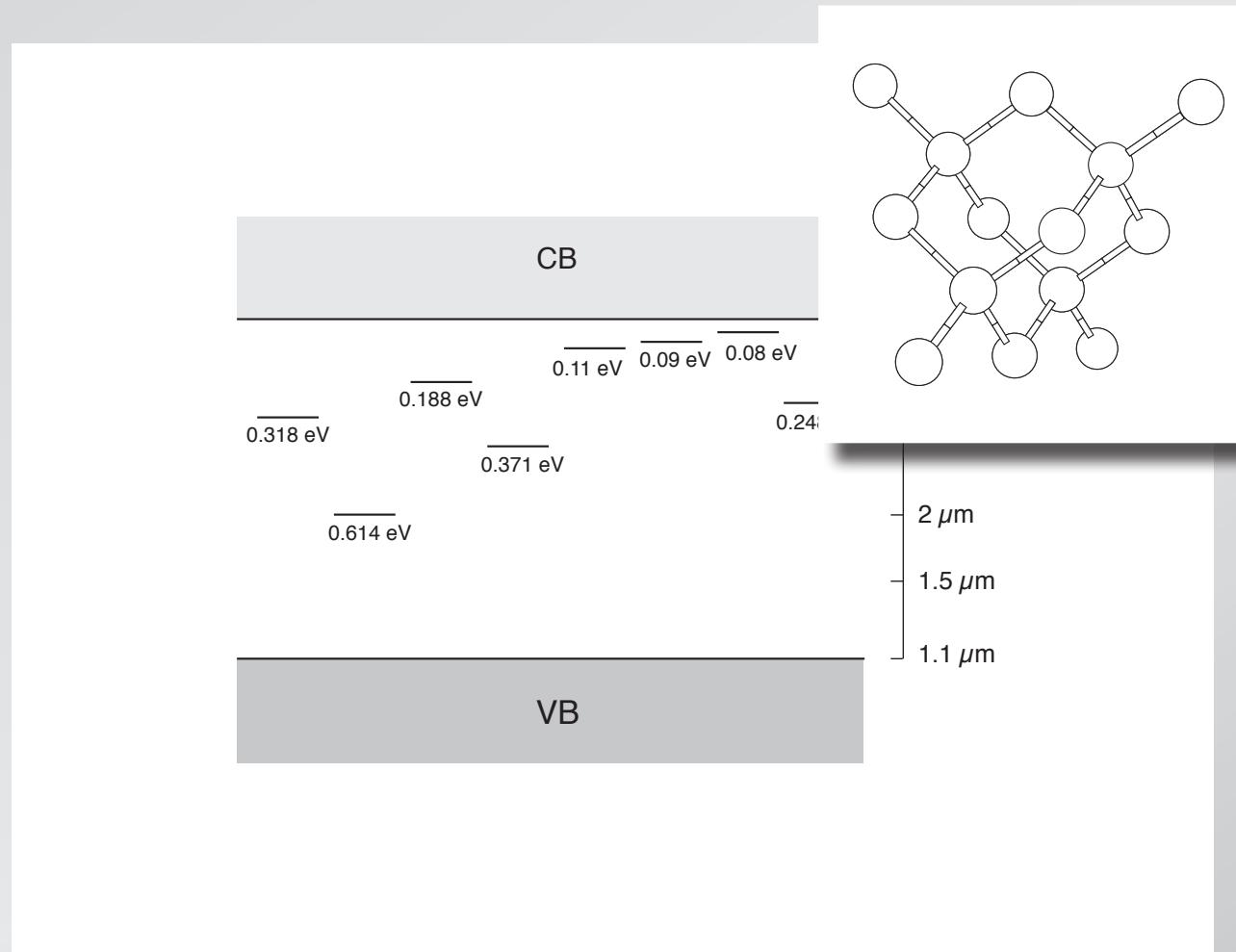


Janzén *et al.*, Phys. Rev. B 29, 1907 (1984)

1 properties

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1 part in 10^6 sulfur introduces donor states in gap

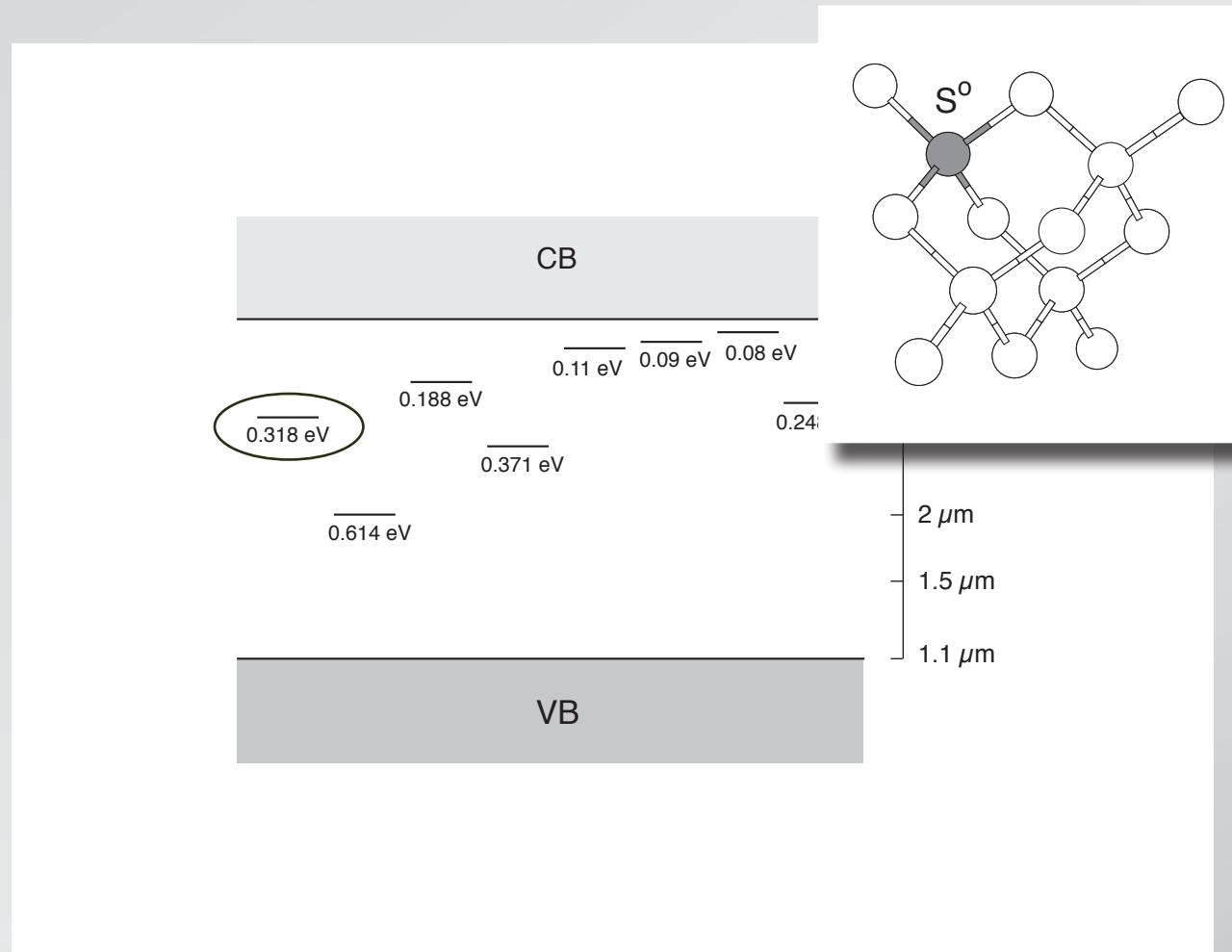


Janzén *et al.*, Phys. Rev. B 29, 1907 (1984)

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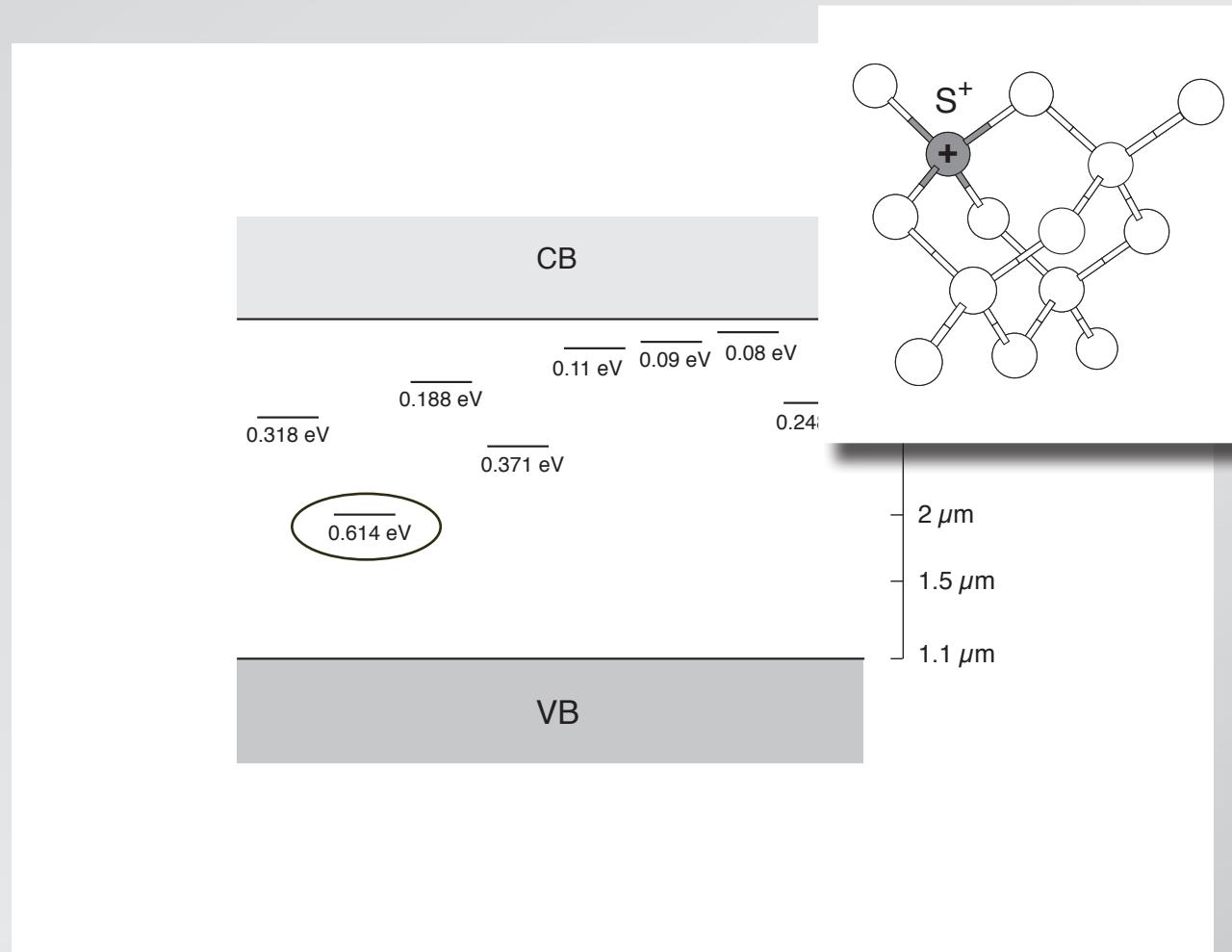


Janzén *et al.*, Phys. Rev. B 29, 1907 (1984)

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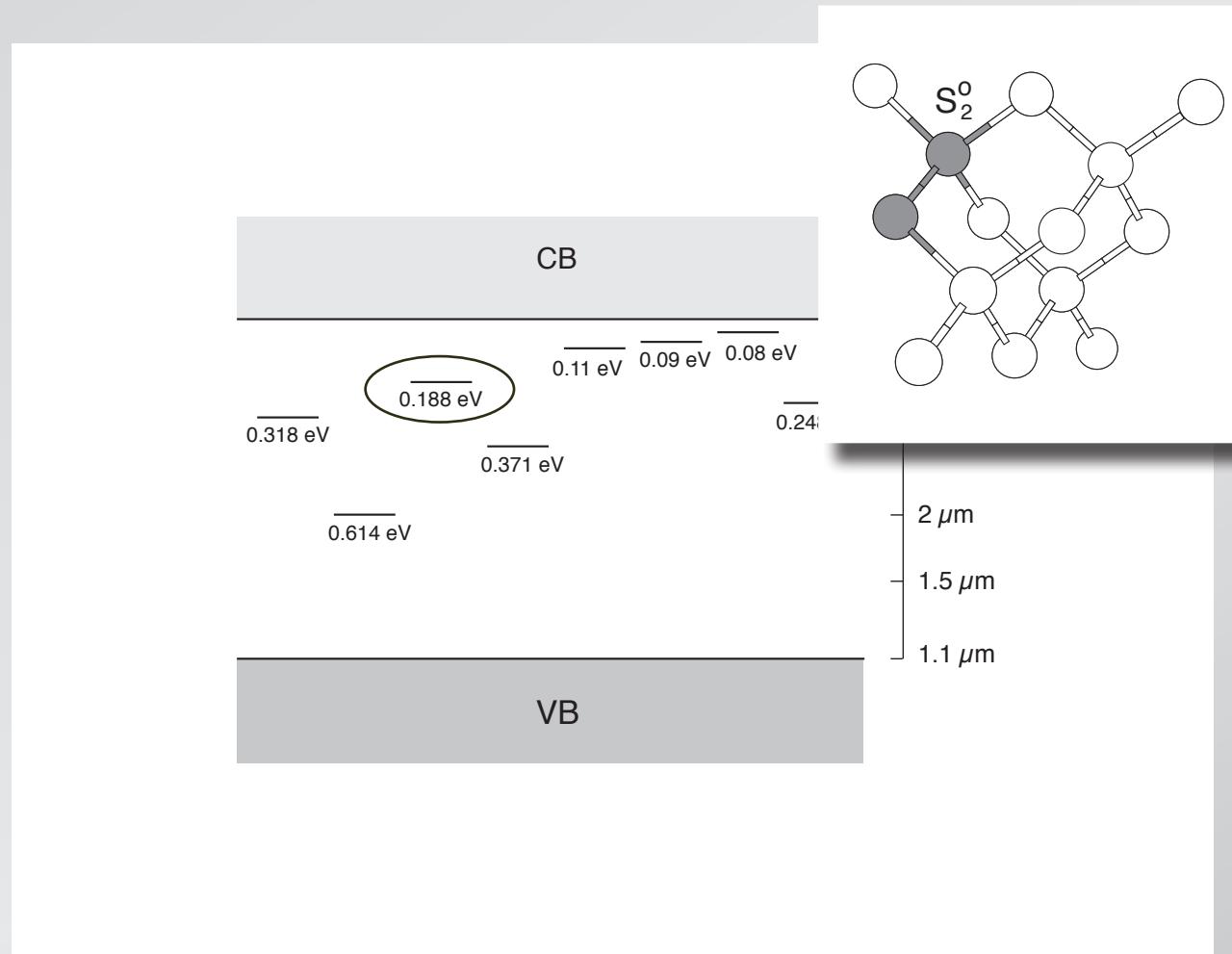


Janzén *et al.*, Phys. Rev. B 29, 1907 (1984)

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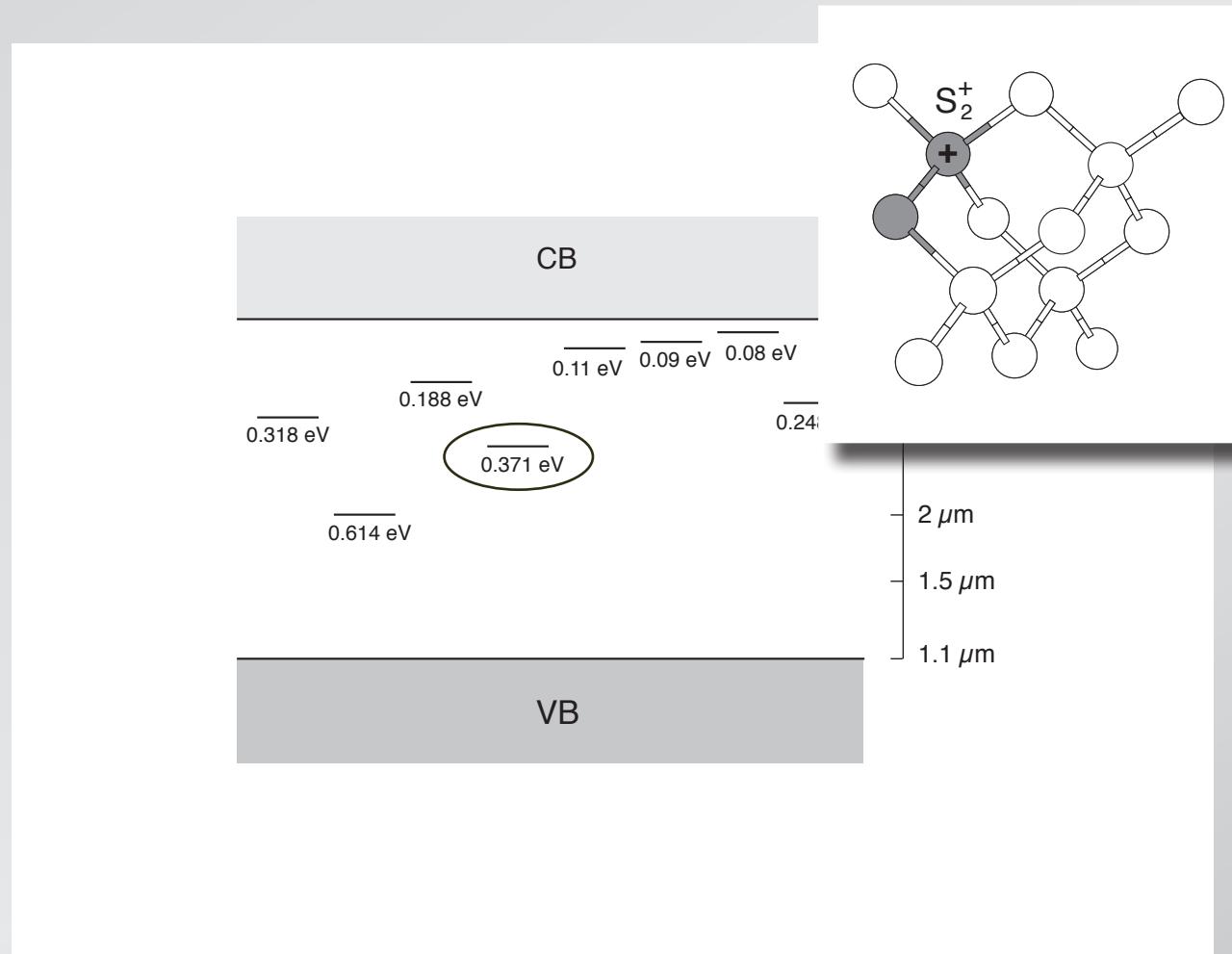


Janzén et al., Phys. Rev. B 29, 1907 (1984)

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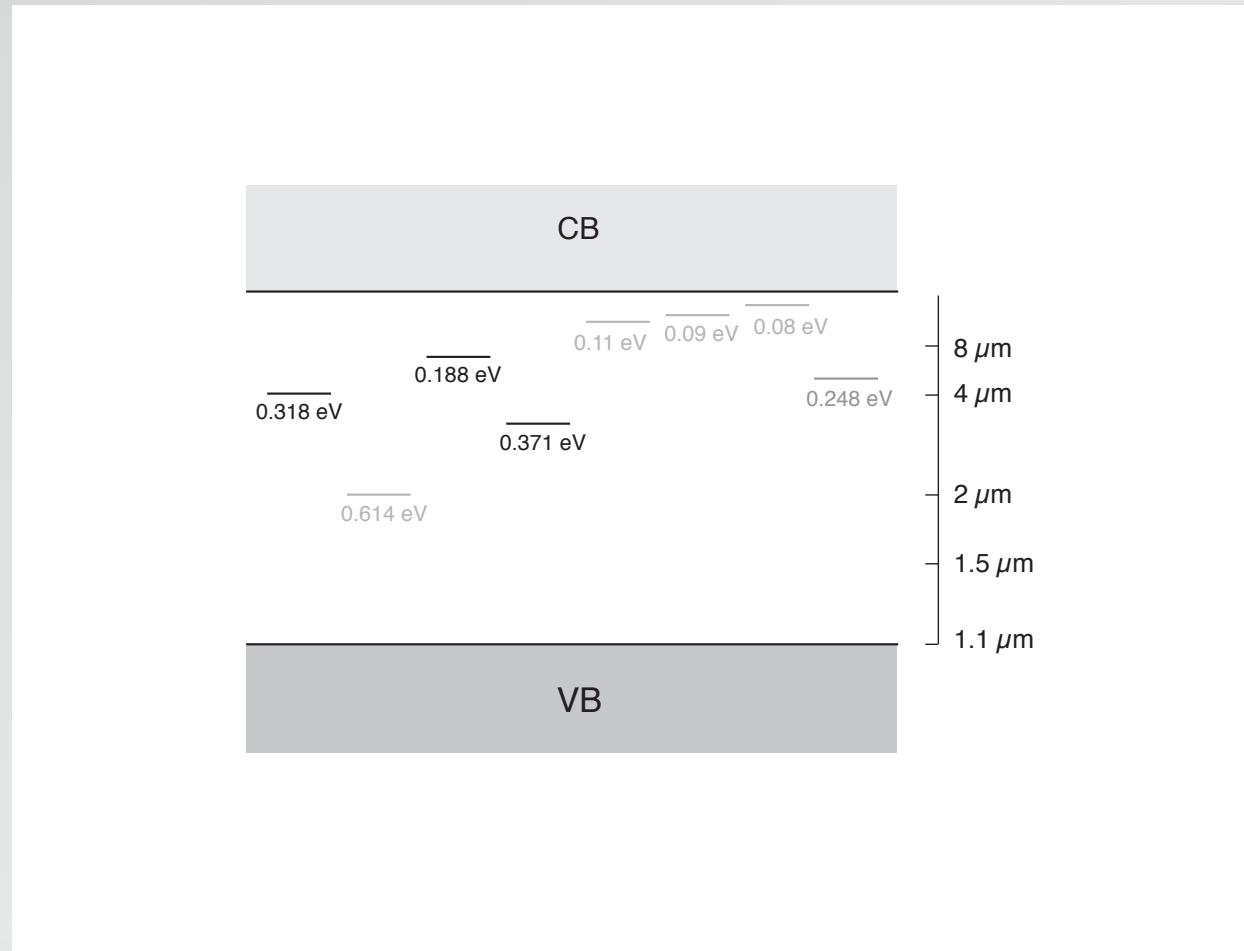


Janzén et al., Phys. Rev. B 29, 1907 (1984)

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1 part in 10^6 sulfur introduces donor states in gap

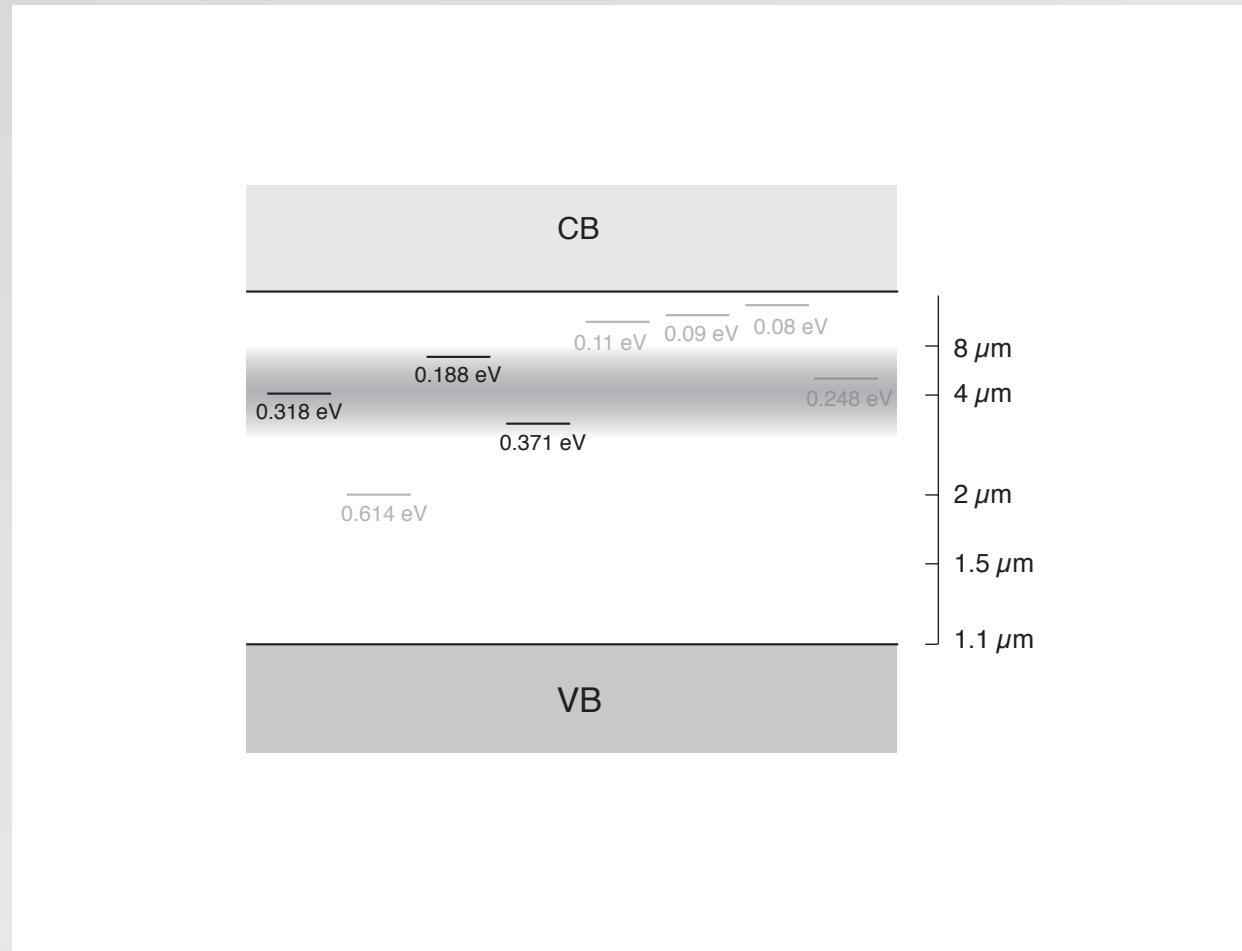


Janzén et al., Phys. Rev. B 29, 1907 (1984)

1 properties

2 intermediate band

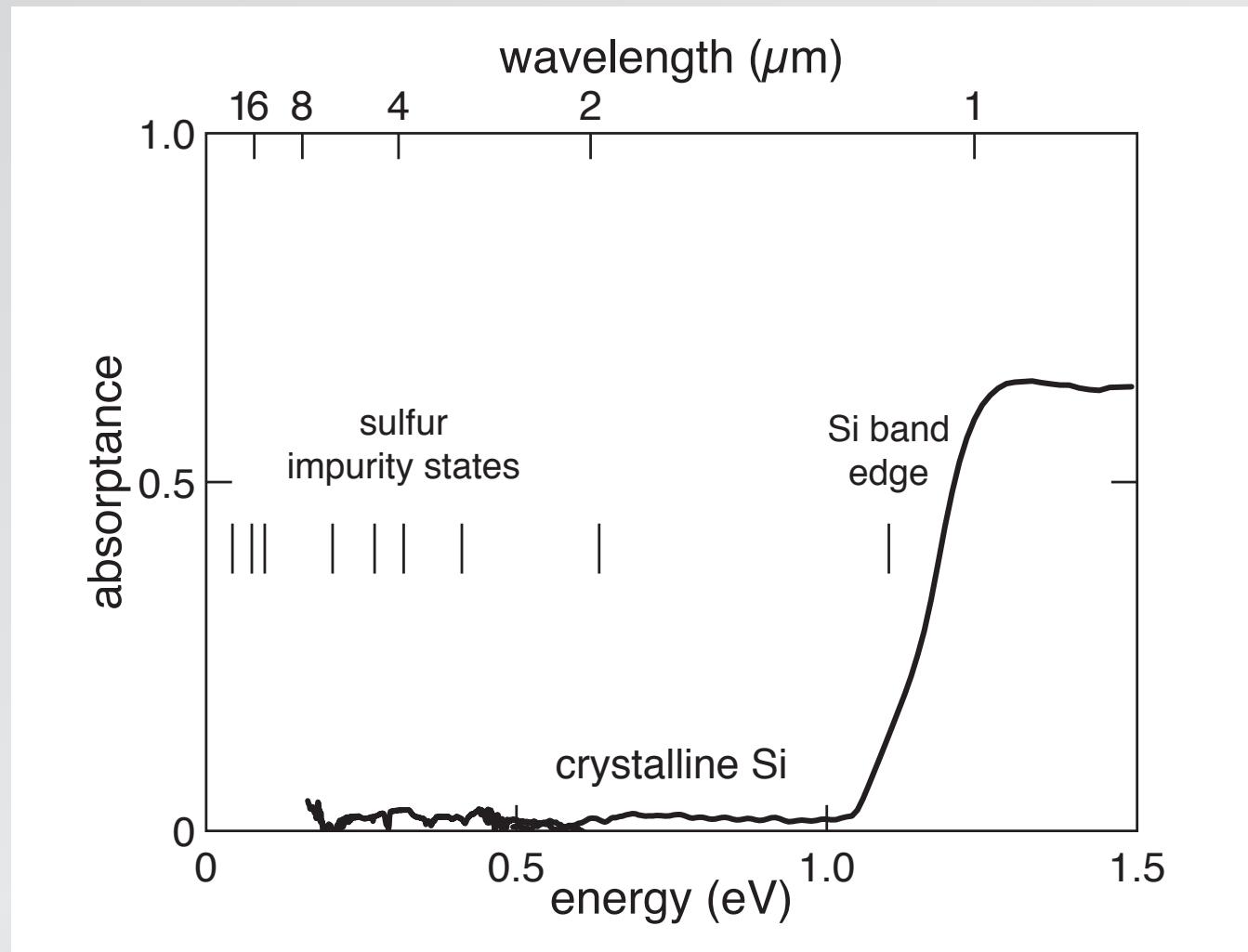
at high concentration states broaden into band



1 properties

2 intermediate band

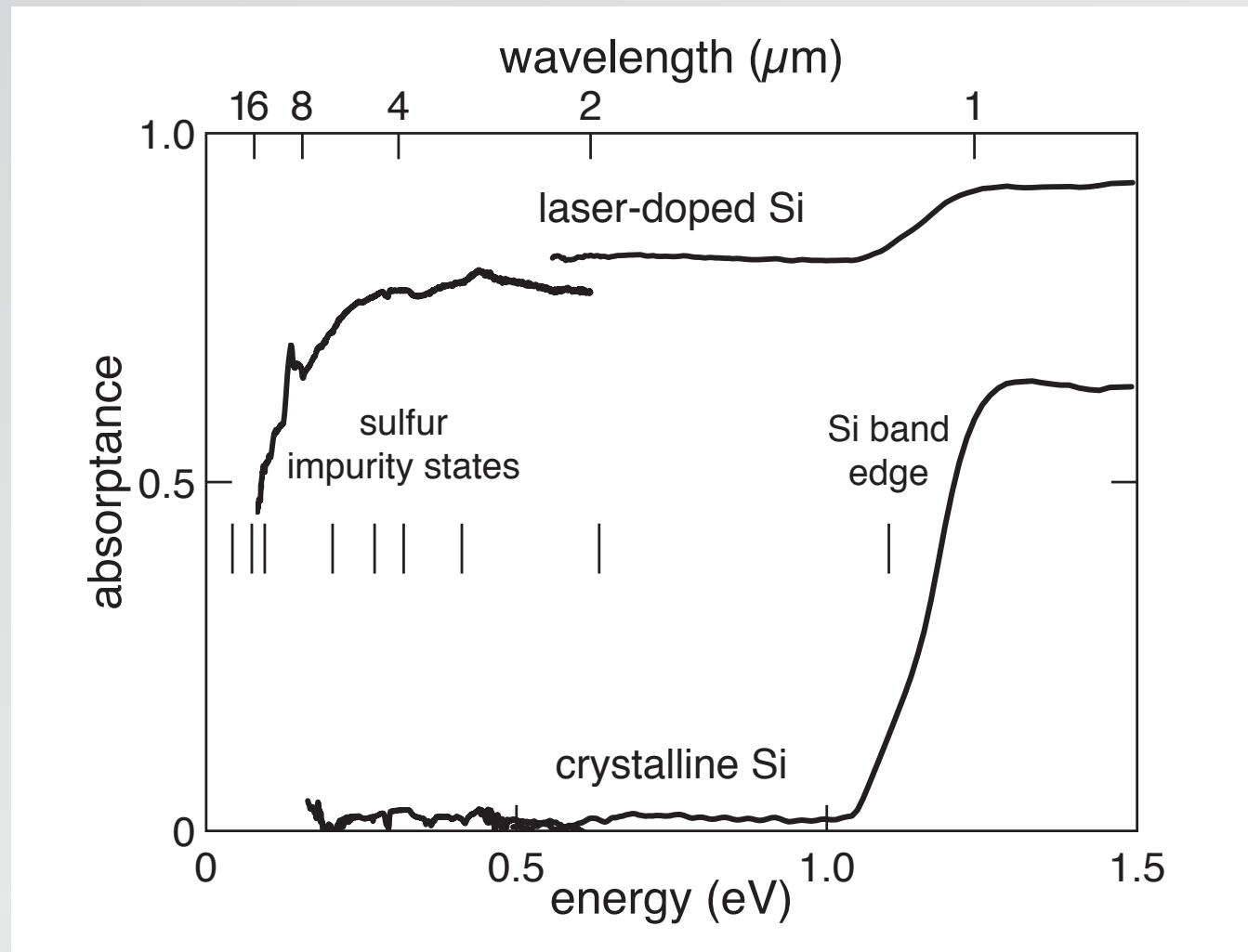
10^{-6} sulfur doping



1 properties

2 intermediate band

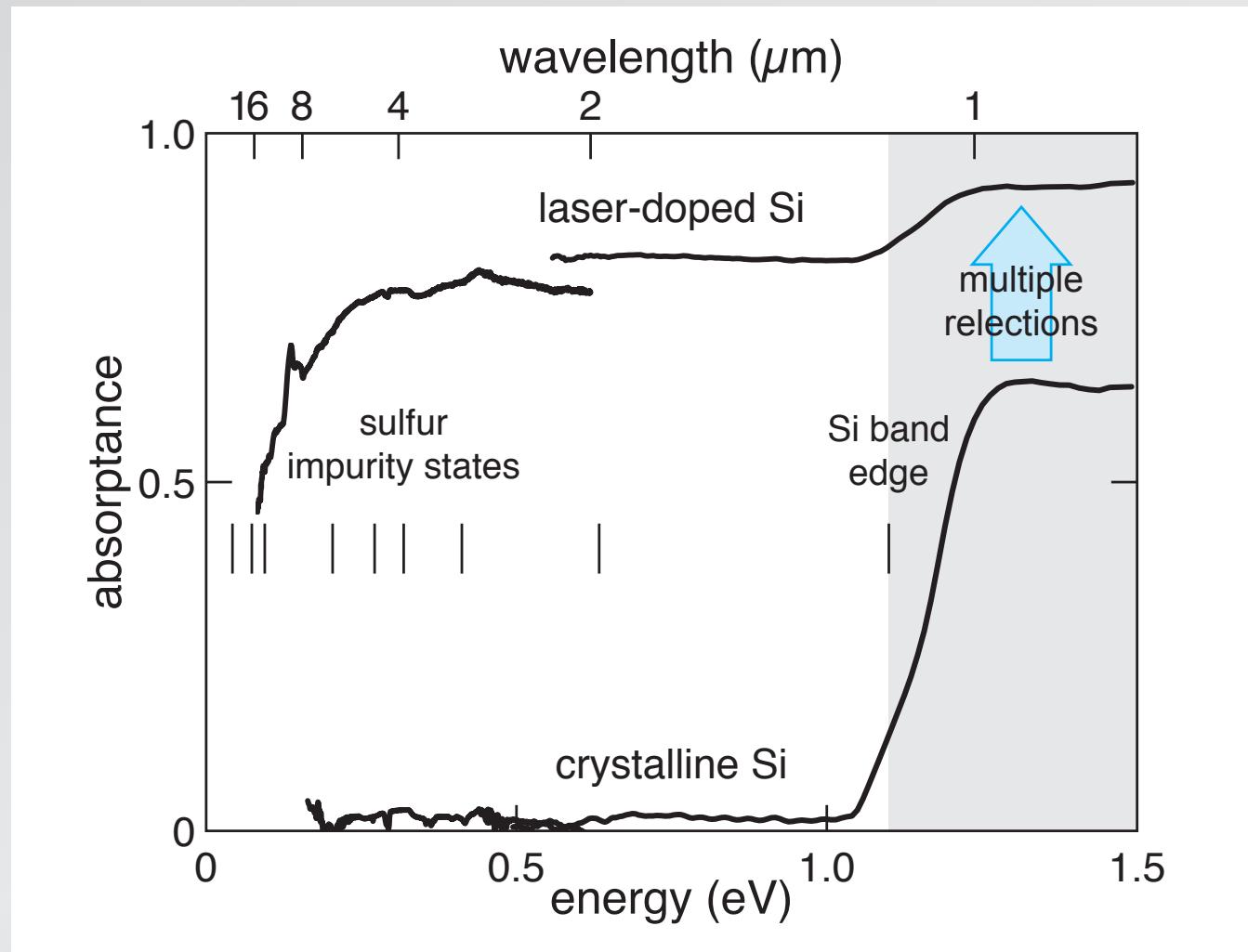
laser-doped S:Si



1 properties

2 intermediate band

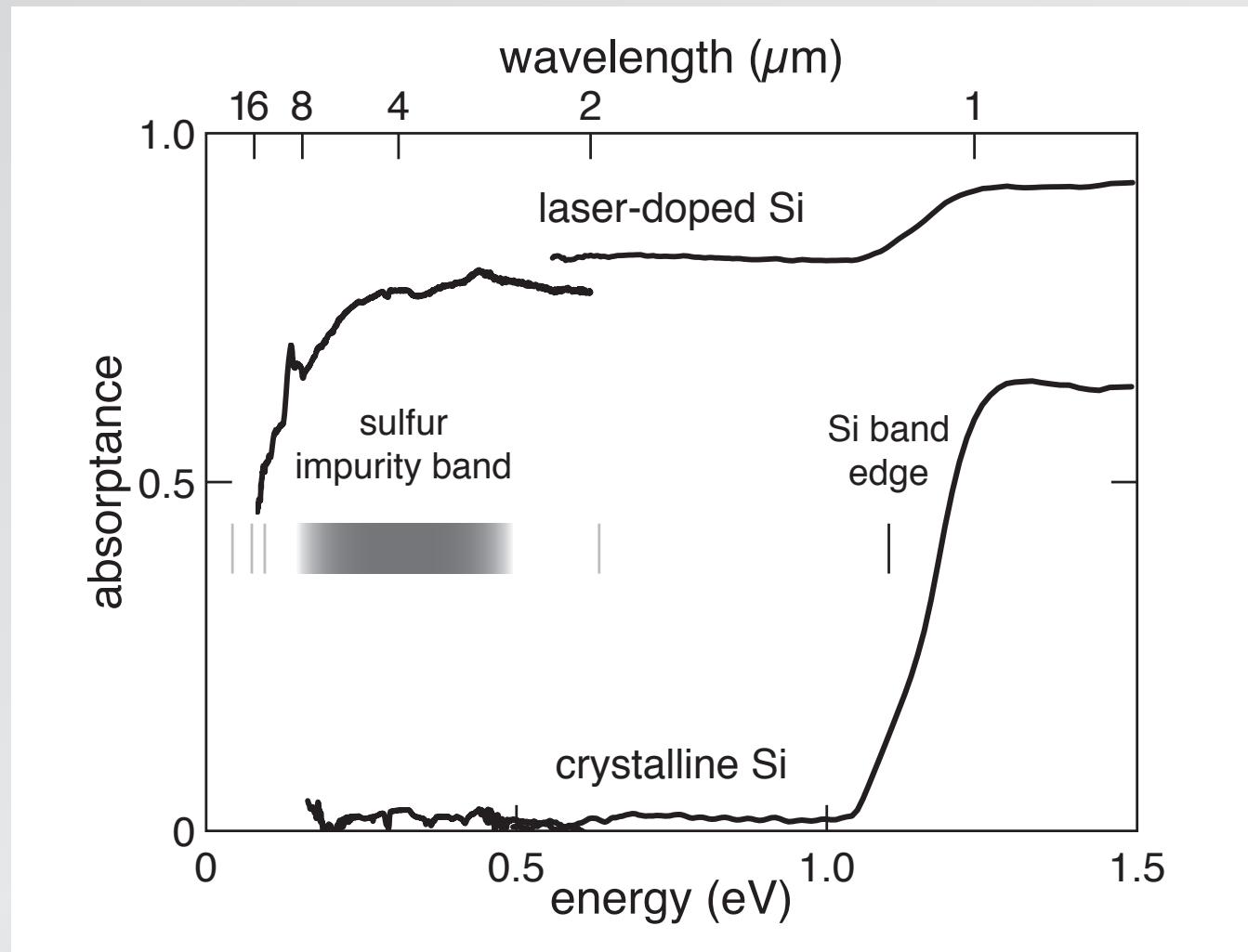
laser-doped S:Si



1 properties

2 intermediate band

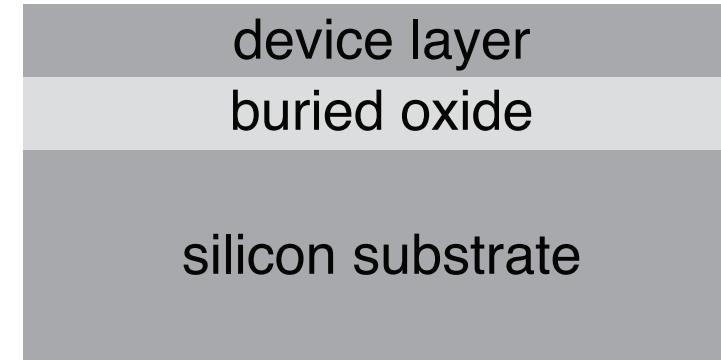
laser-doped S:Si



1 properties

2 intermediate band

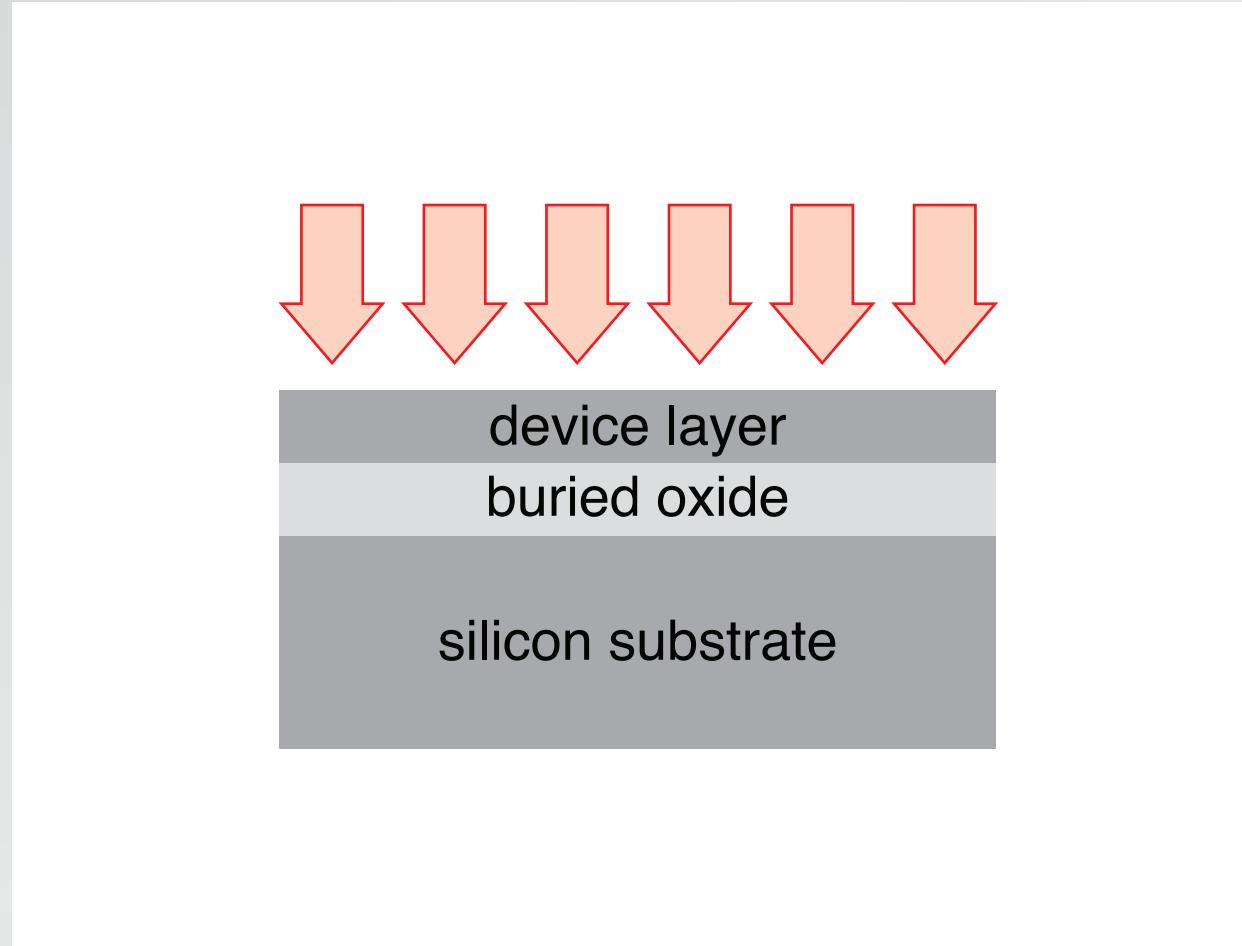
isolate surface layer for Hall measurements



1 properties

2 intermediate band

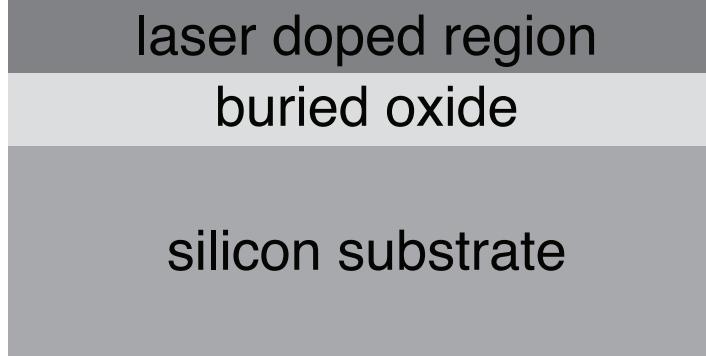
isolate surface layer for Hall measurements



1 properties

2 intermediate band

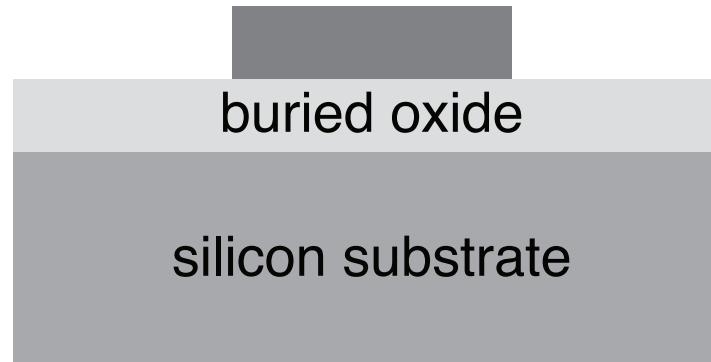
isolate surface layer for Hall measurements



1 properties

2 intermediate band

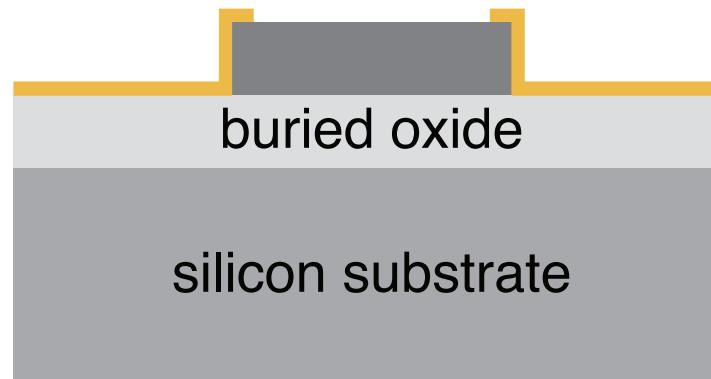
isolate surface layer for Hall measurements



1 properties

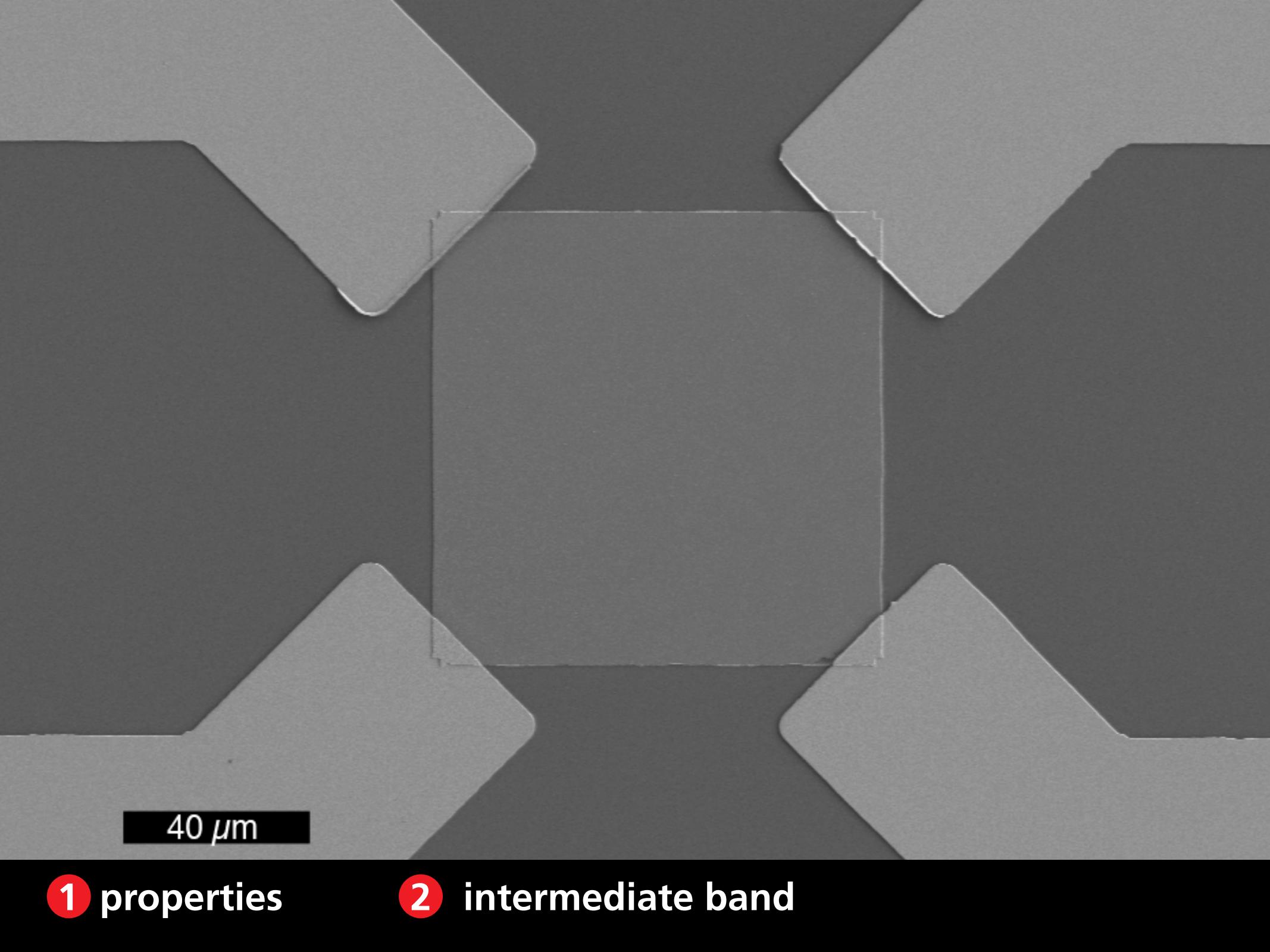
2 intermediate band

isolate surface layer for Hall measurements



1 properties

2 intermediate band

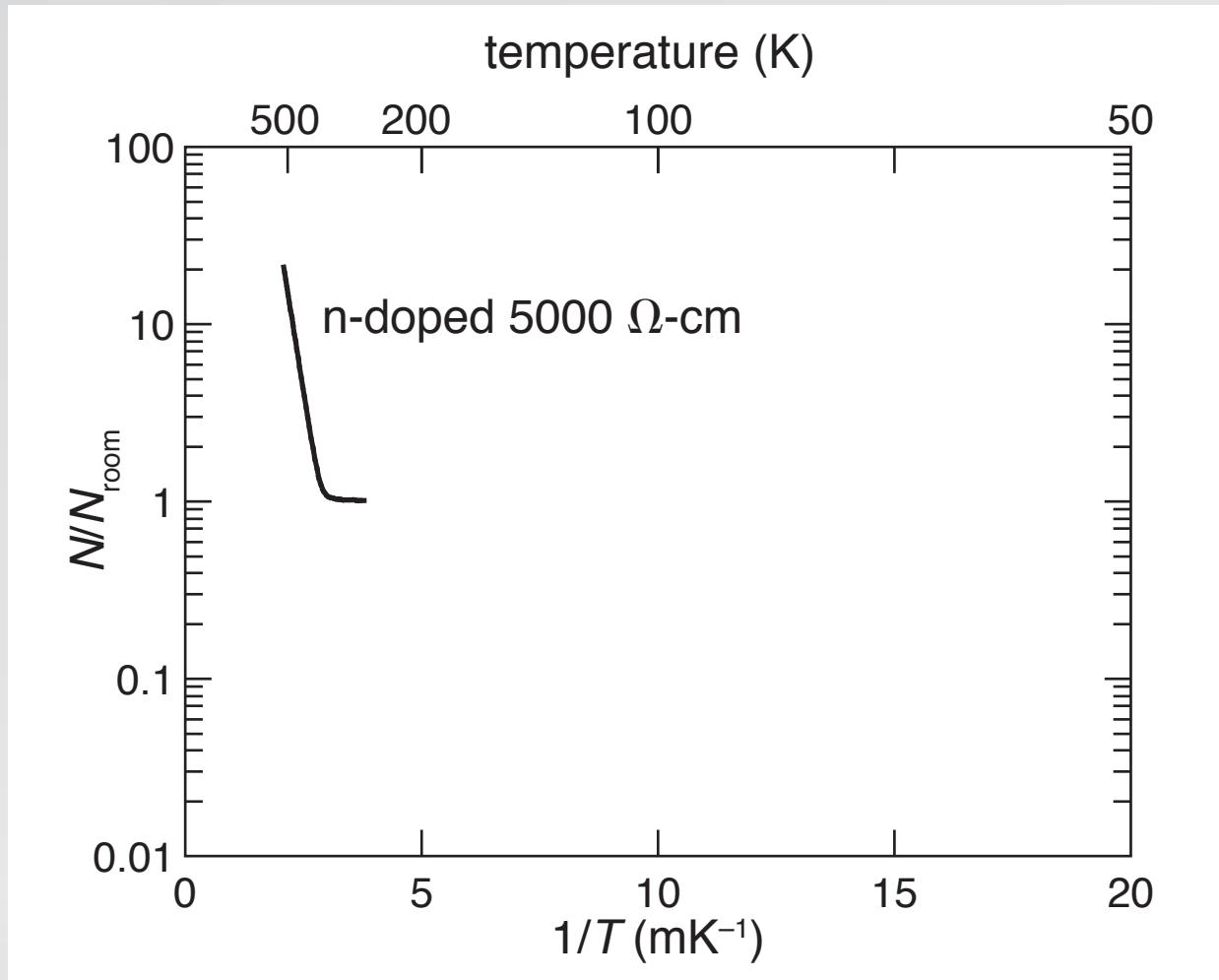


40 μm

1 properties

2 intermediate band

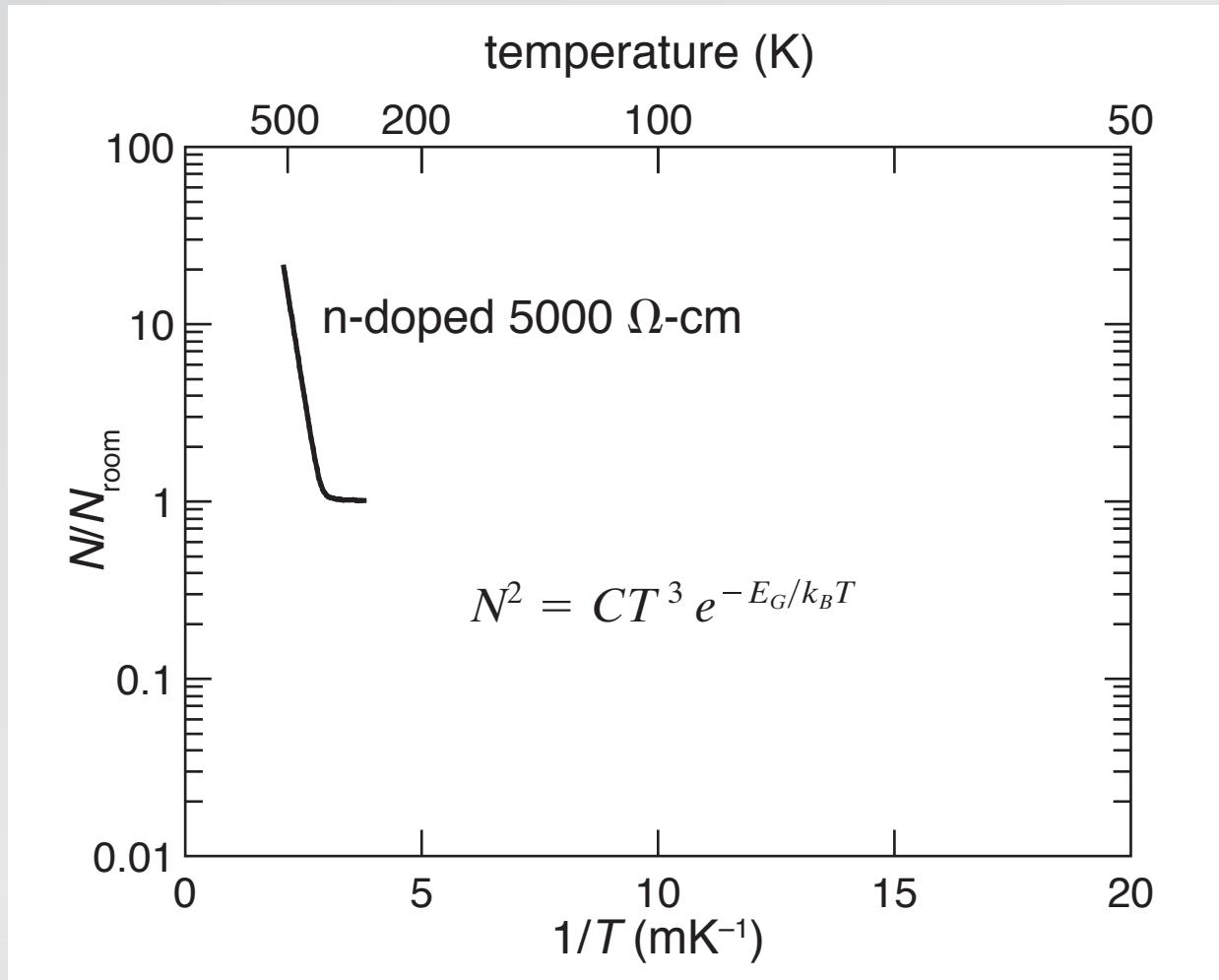
Hall measurements



1 properties

2 intermediate band

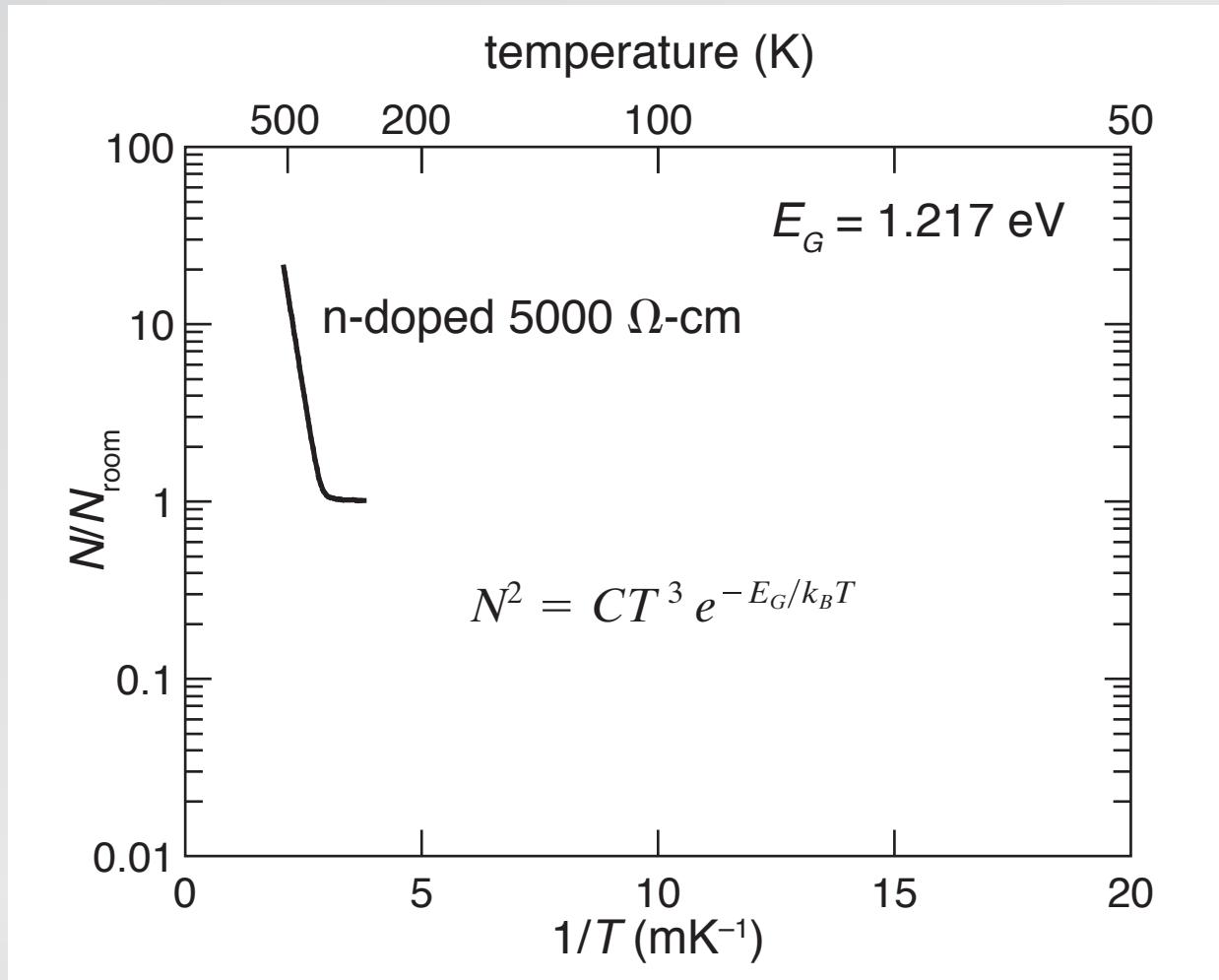
Hall measurements



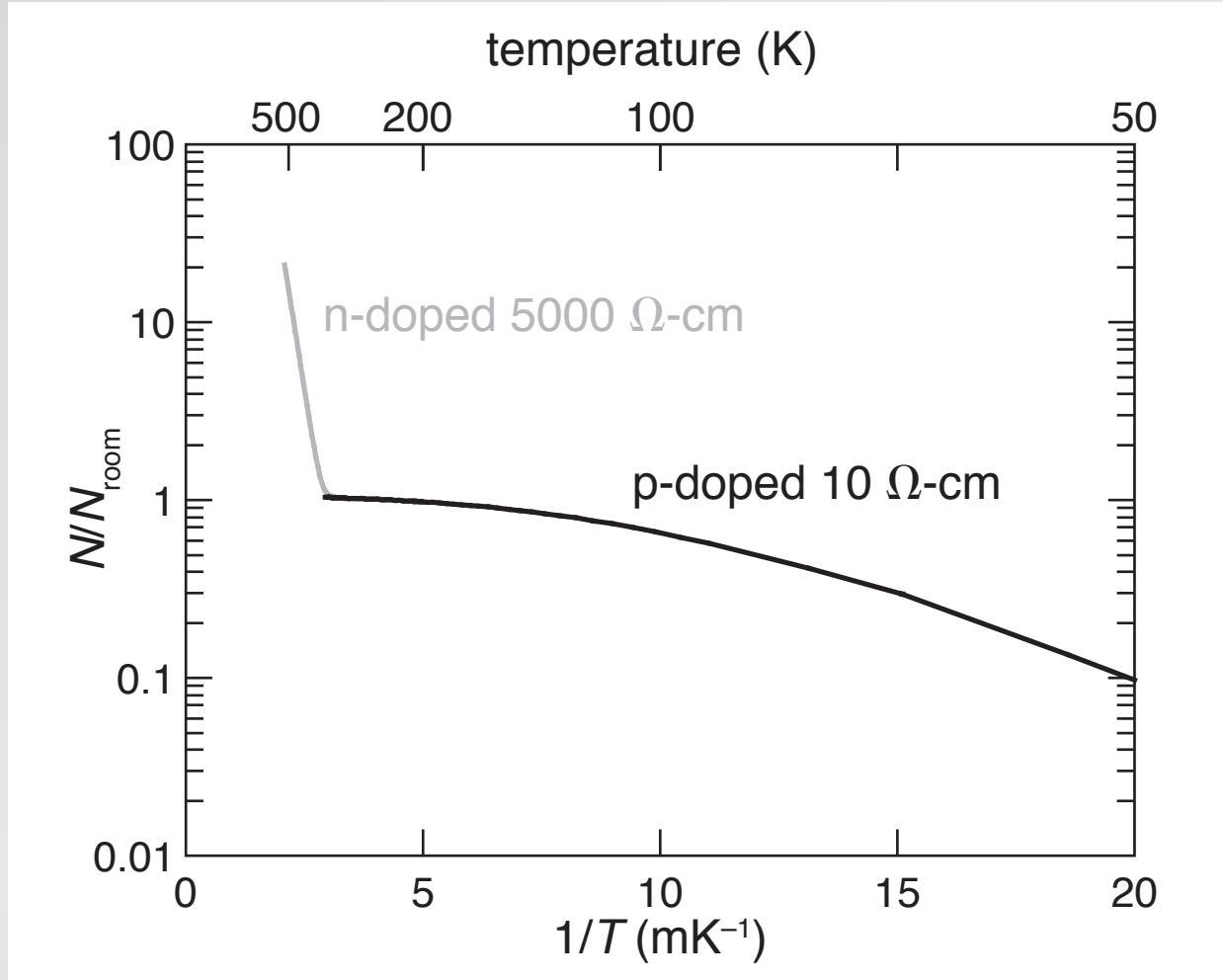
1 properties

2 intermediate band

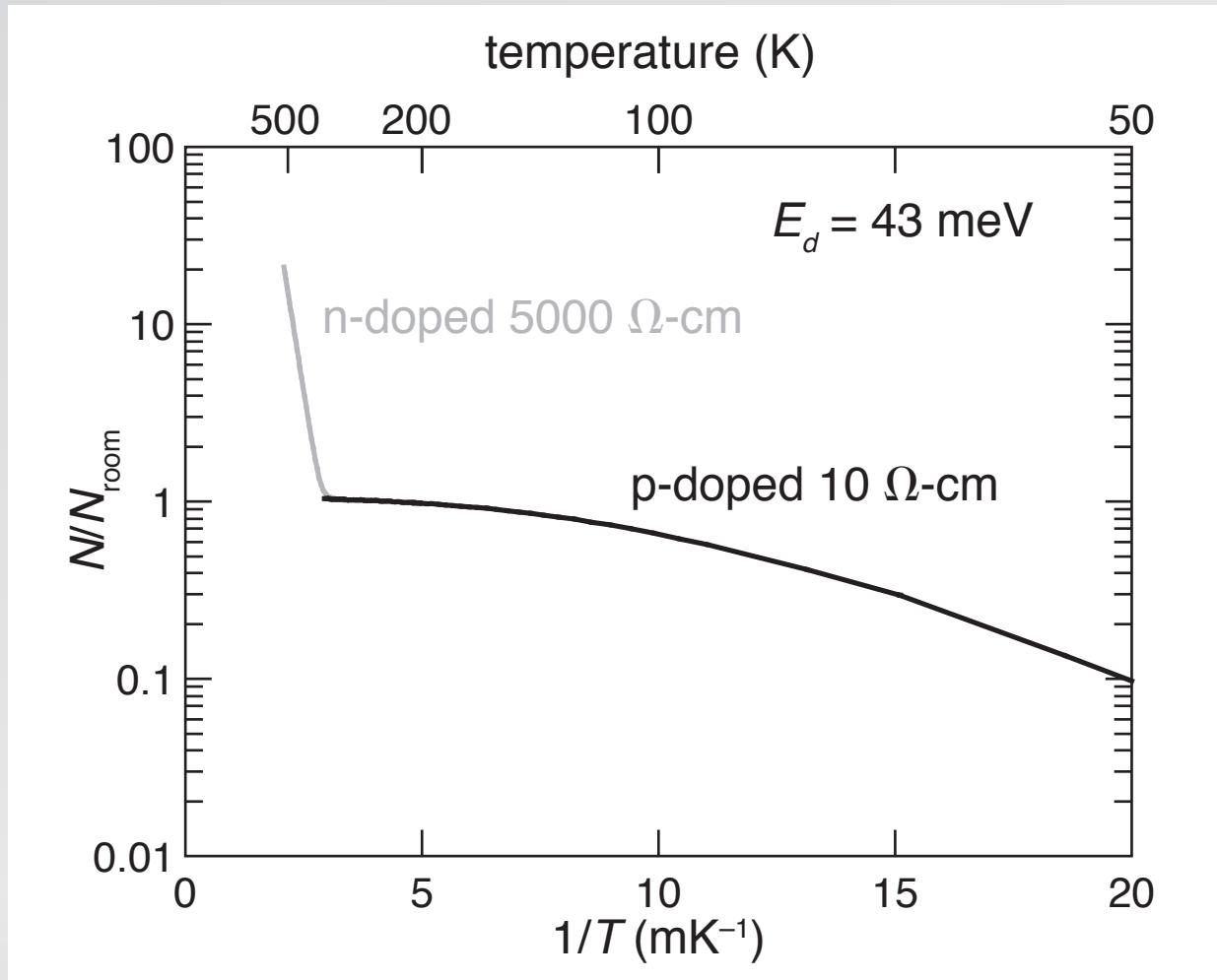
Hall measurements



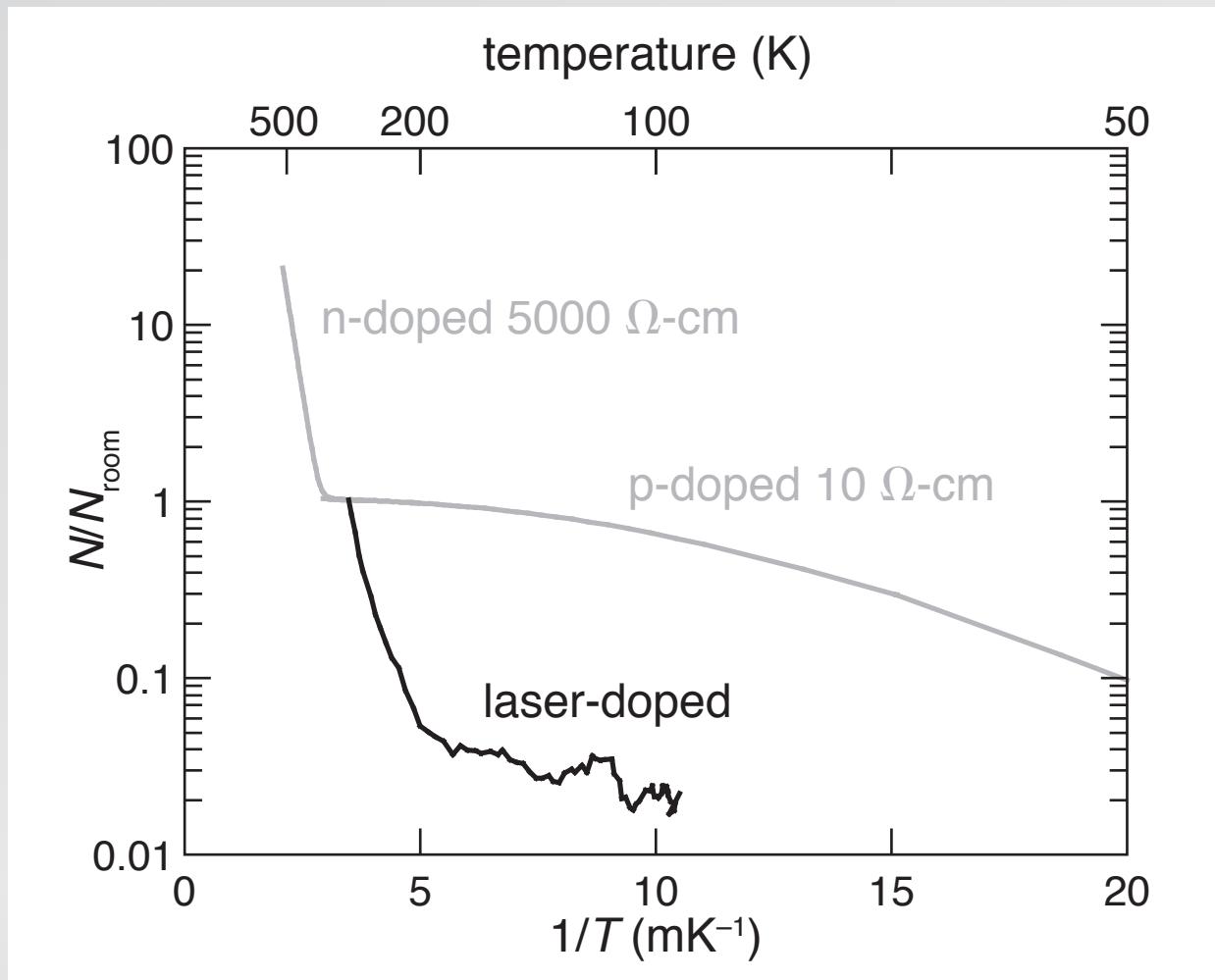
Hall measurements



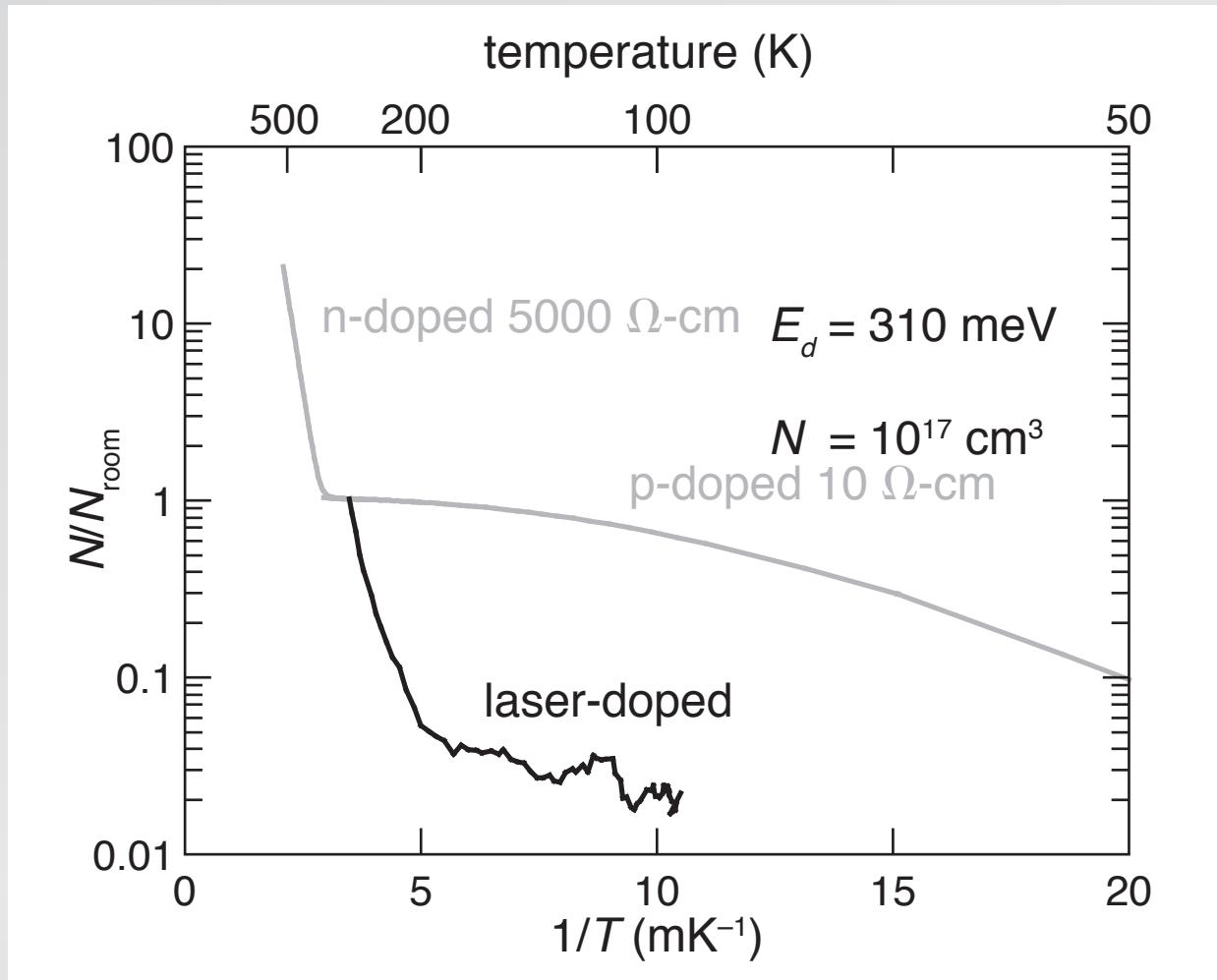
Hall measurements



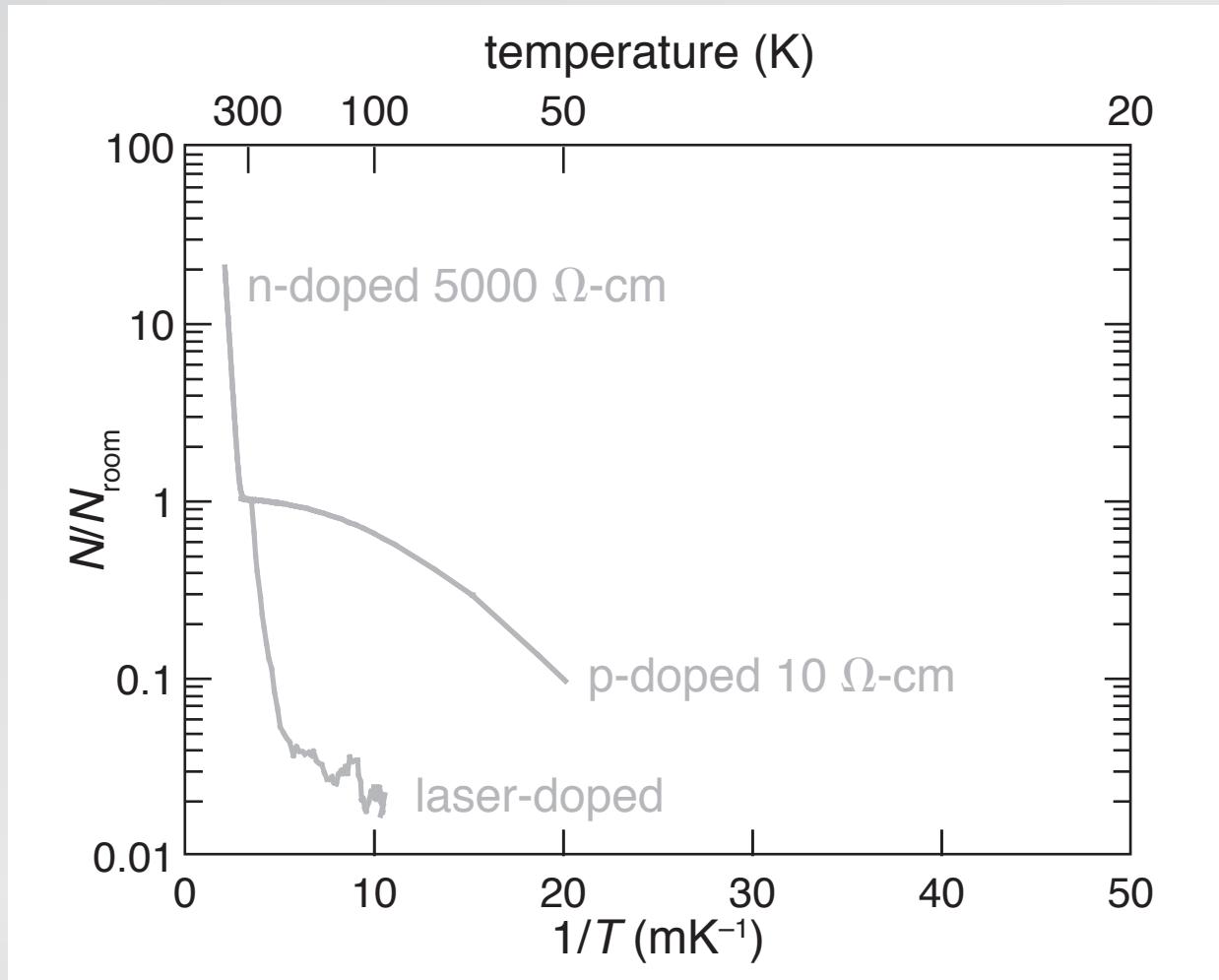
Hall measurements



Hall measurements



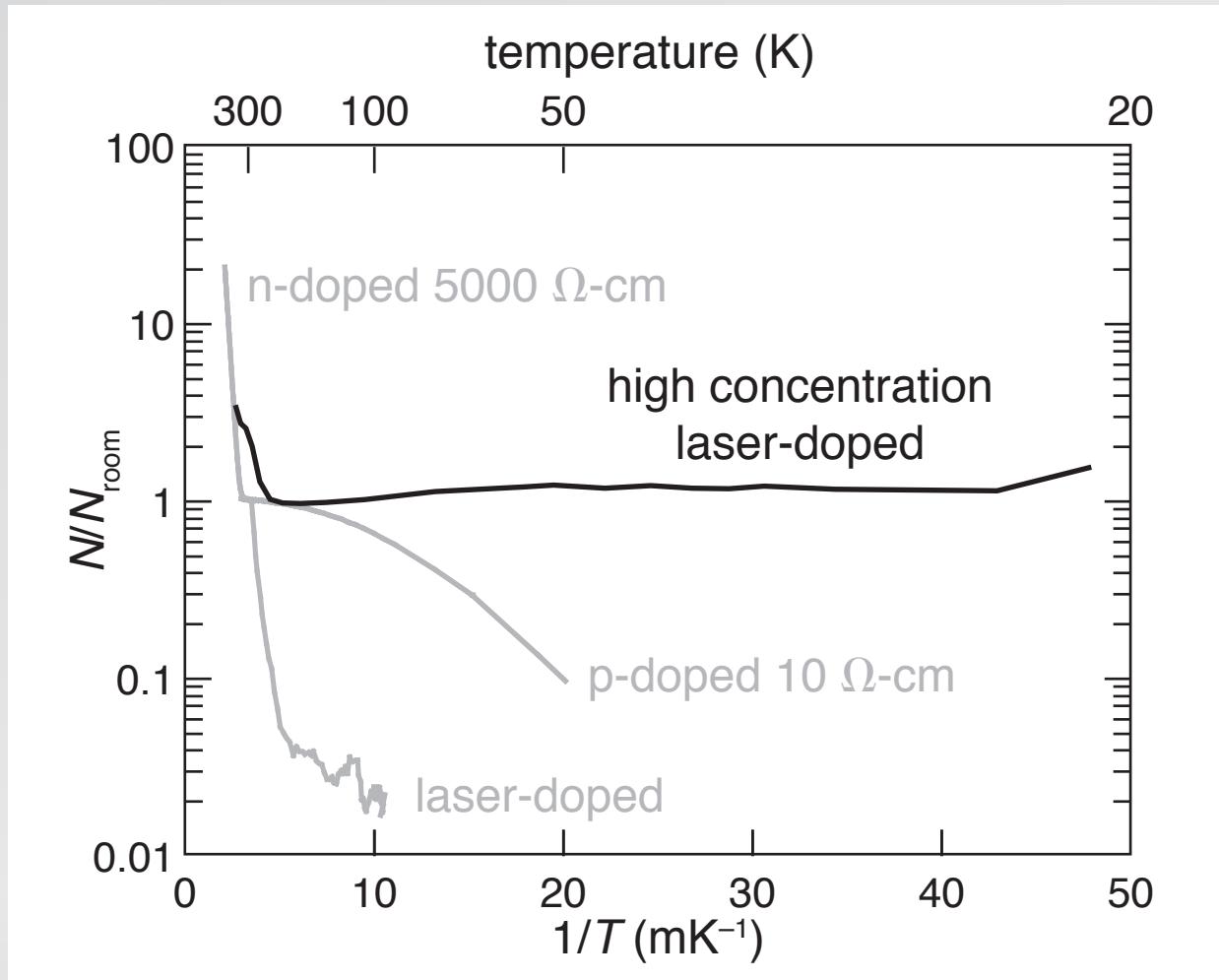
Hall measurements



1 properties

2 intermediate band

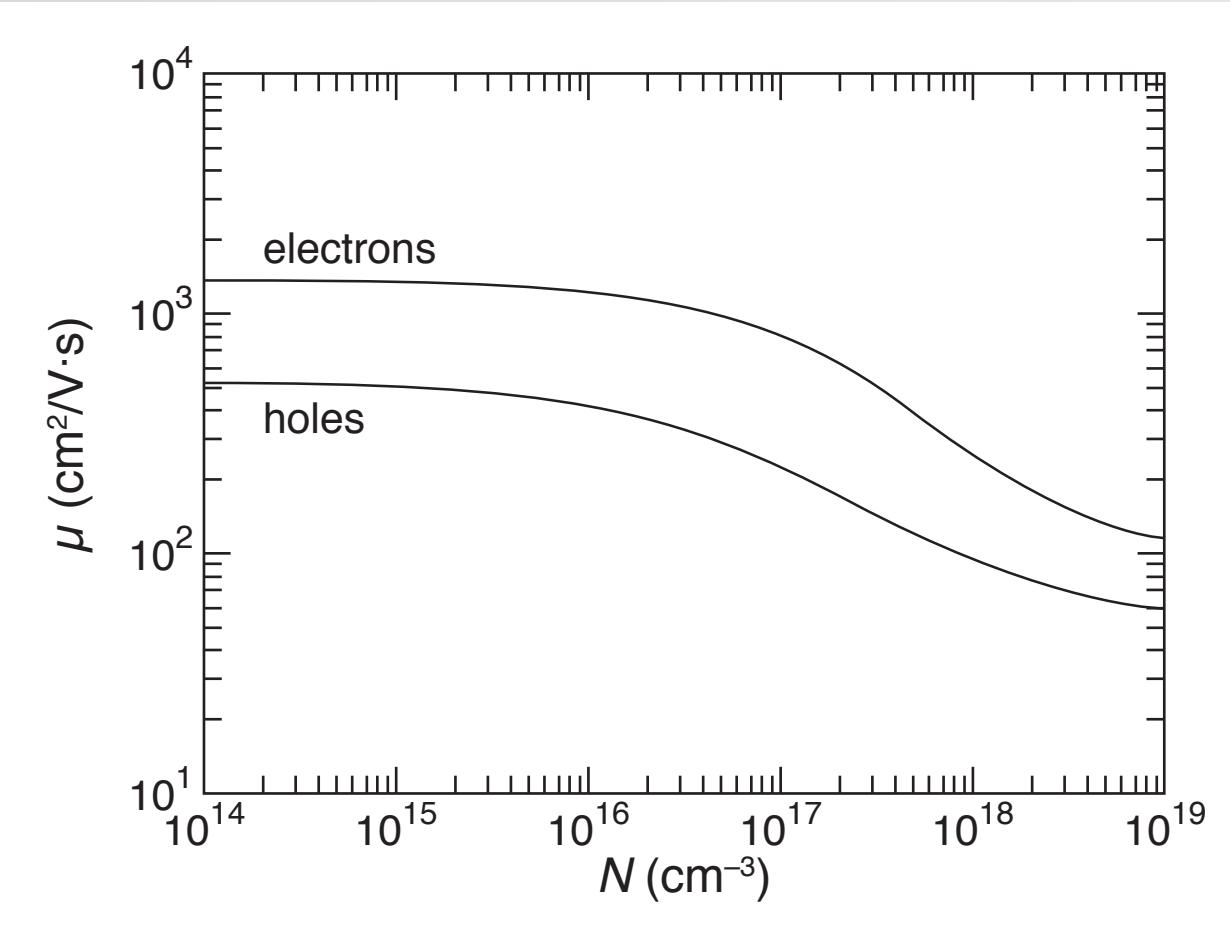
Hall measurements



1 properties

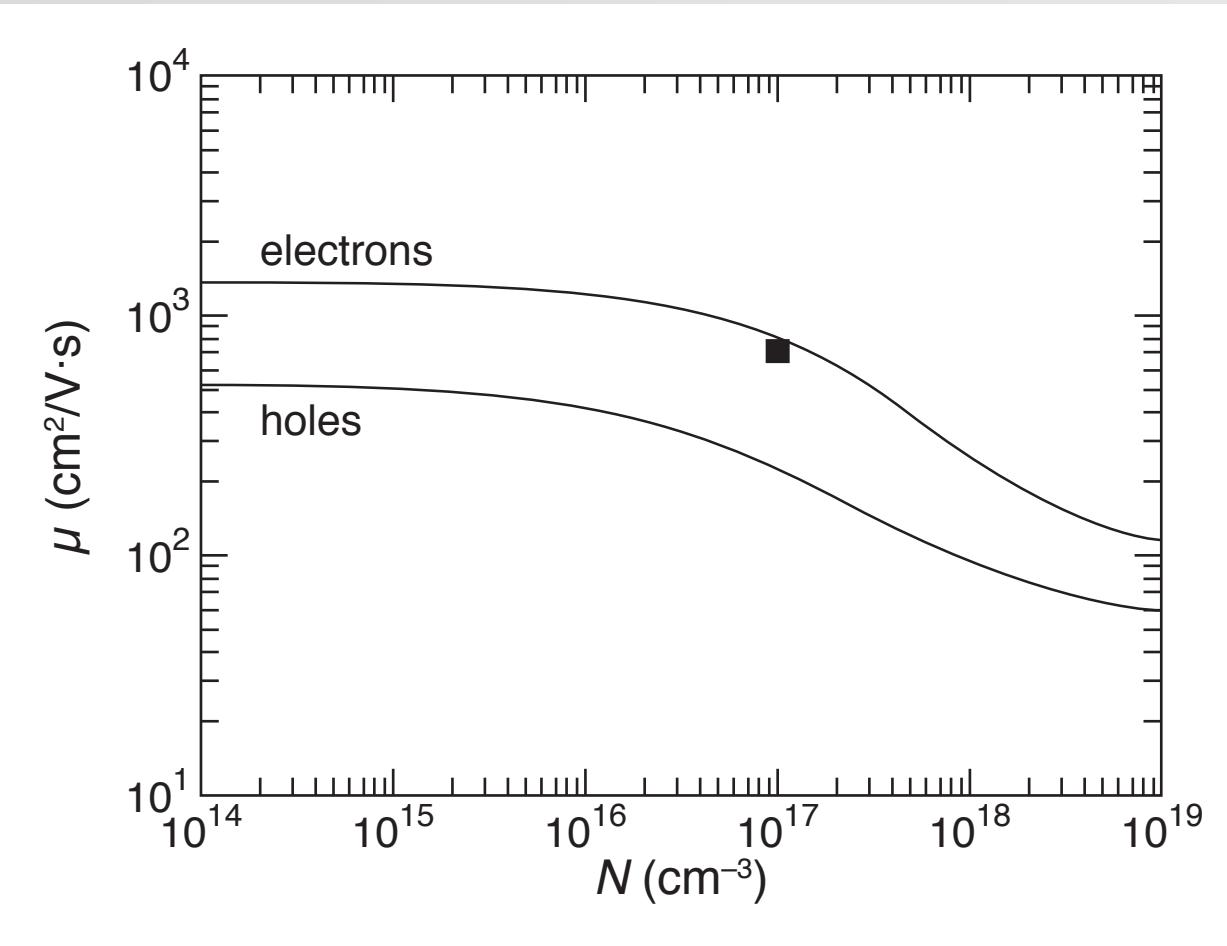
2 intermediate band

majority carrier mobility



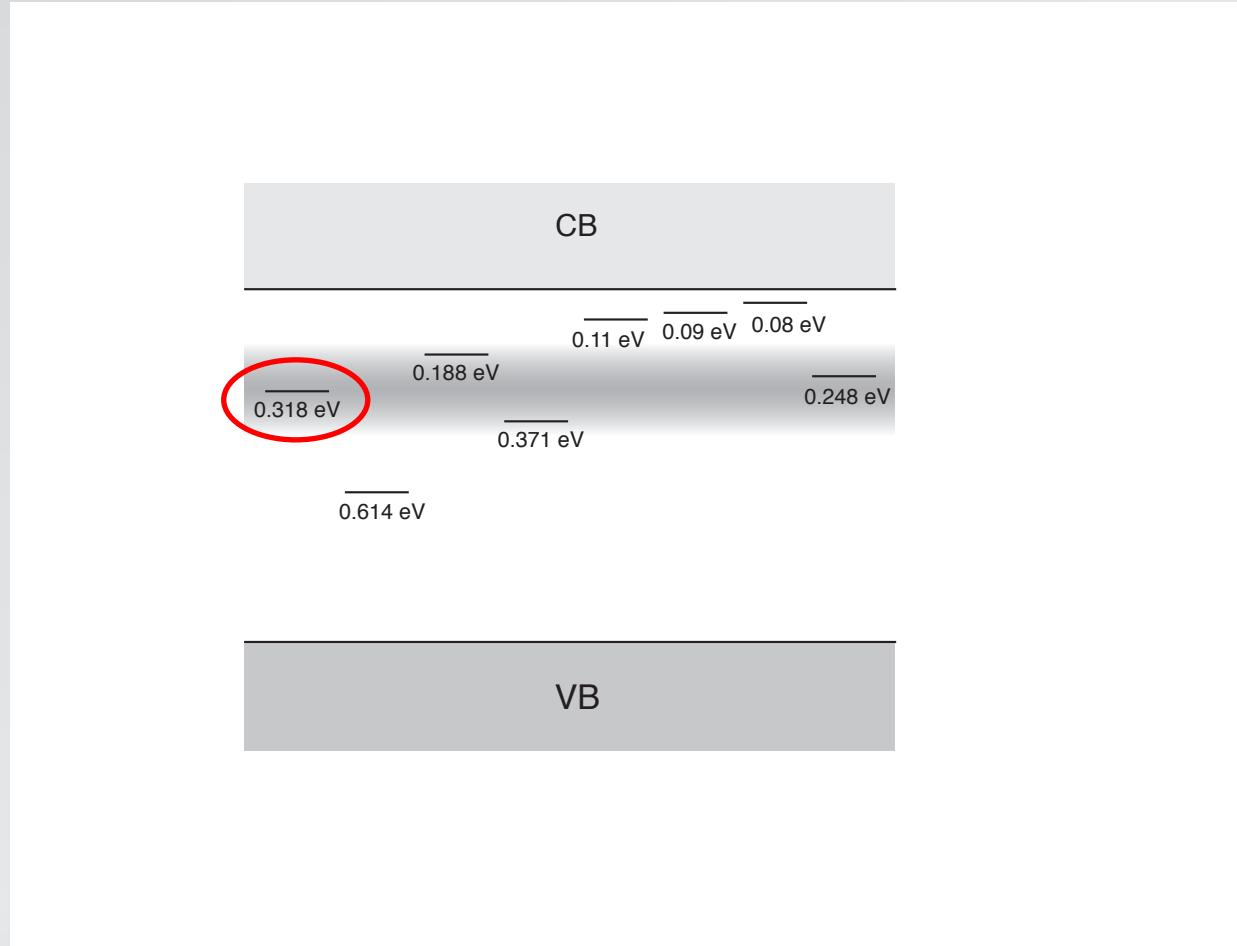
Caughey et al., Proc. IEEE 55, 2192 (1967)

majority carrier mobility



Caughey et al., Proc. IEEE 55, 2192 (1967)

impurity (donor) band centered at 310 meV



1 properties

2 intermediate band

Insulator-to-Metal Transition in Selenium-Hyperdoped Silicon: Observation and Origin

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(Received 14 October 2011; published 11 January 2012)

Hyperdoping has emerged as a promising method for designing semiconductors with unique optical and electronic properties, although such properties currently lack a clear microscopic explanation. Combining computational and experimental evidence, we probe the origin of sub-band-gap optical absorption and metallicity in Se-hyperdoped Si. We show that sub-band-gap absorption arises from direct defect-to-conduction-band transitions rather than free carrier absorption. Density functional theory predicts the Se-induced insulator-to-metal transition arises from merging of defect and conduction bands, at a critical concentration, demonstrate that correlation is important to describing the transition accurately, and suggest that it is a classic impurity-driven Mott transition.

PACS numbers: 71.30.+h, 61.72.sd, 73.61.Cw, 78.20.Bh

Of all the experimentally measurable physical properties of materials, electronic conductivity exhibits the largest variation, spanning a factor of 10^{31} from the best metals to the strongest insulators [1]. Over the last century, the puzzle of why some materials are conductors and others insulators, and the mechanisms underlying the transformation from one to the other, have been carefully scrutinized; yet even after such a vast body of research over such a long period, the subject remains the object of controversy. In 1956, Mott introduced a model for the insulator-to-metal transition (IMT) in doped semiconductors, in which long-ranged electron correlations are the driving force [2]. Hyperdoping (doping beyond the solubility limit) creates IMTs in semiconductors. In this Letter, we identify a new materials playground to explore defect-mediated IMTs in silicon hyperdoped with selenium to concentrations exceeding 10^{20} cm^{-3} (compared to the equilibrium solubility limit [3] of about 10^{16} cm^{-3}) and we detailed nature of the transition with both transition. We find that the IMT is additional, we

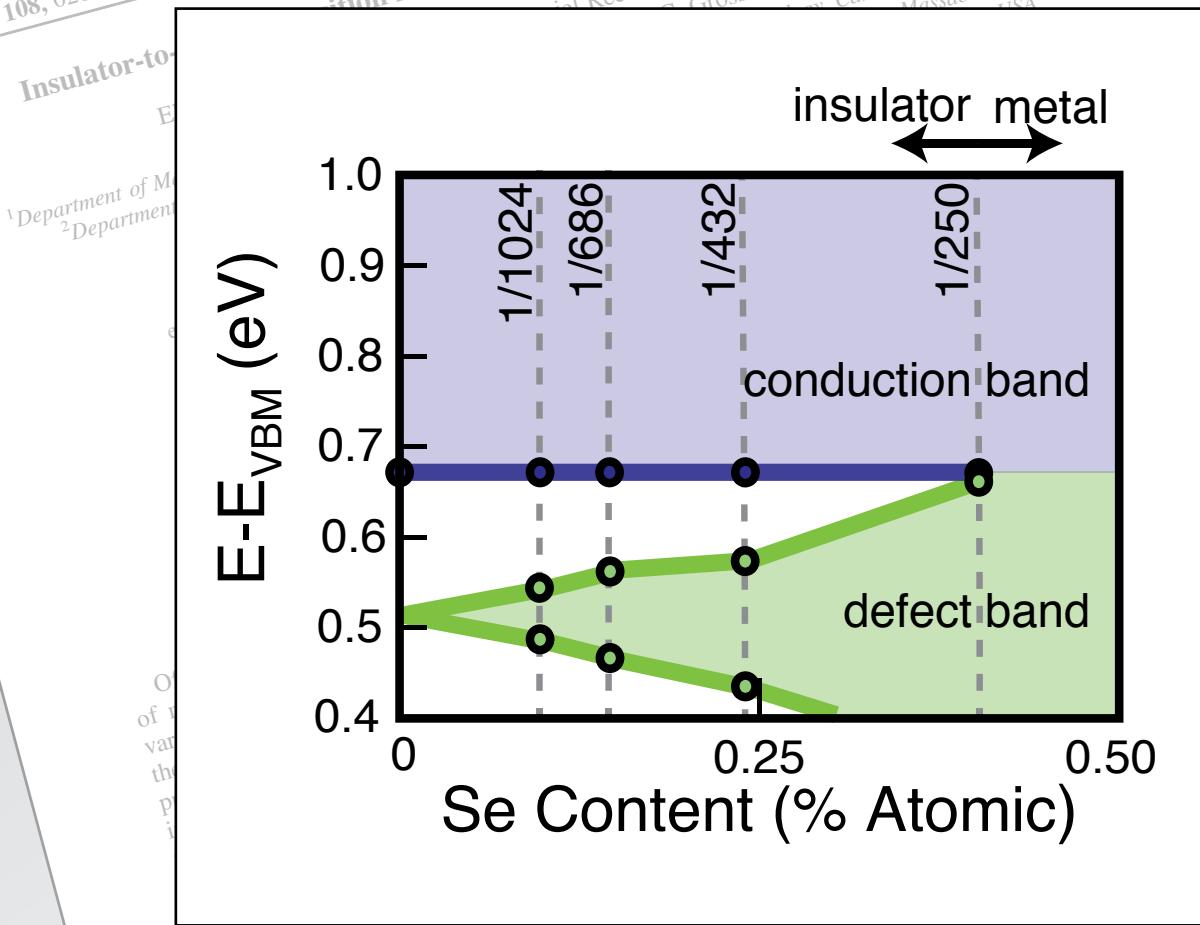
silicon appears to justify such interest. While isolated S and Se dopants are well-established deep double donors in silicon [3,14], the enhanced optical properties of hyperdoped silicon (in which these chalcogenic impurities are present at much higher concentrations) are not yet well understood. Further, unlike the prototypical system of phosphorus-doped silicon for which the IMT has been extensively studied and characterized [15,16], there are very few studies of an IMT resulting from deep defects such as chalcogens [17].

We prepared Se-doped silicon (Se:Si) samples using ion implantation followed by nanosecond pulsed-laser melting (PLM) and rapid resolidification. The PLM process enables chalcogen doping with concentrations exceeding 1% atomic; such samples exhibit unexplained optical properties including broad, featureless absorption of photons with energy lower than the band gap of silicon [9]. Silicon substrates (boron doped, $\rho \approx 25 \Omega \text{ cm}$) were ion implanted with Se to nominal doses of 3×10^{15} and $1 \times 10^{16} \text{ cm}^2$ using an ion beam energy of 176 keV. The implanted samples were exposed to four laser pulses (fluences of 1.7, 1.7, 1.7 and 1.8 J cm^{-2}). This fluence regimen results in a slightly shallower dopant profile, and higher Se concentration, than reported previously [18]. The 1.8 J cm^{-2} laser pulse, which is electrically isolated from the previous pulse, creates a melt layer $1 \mu\text{m}$ thick, as measured

DOI: [10.1103/PhysRevLett.108.026401](https://doi.org/10.1103/PhysRevLett.108.026401)

DFT calculations

PRL 108, 026401 (2012)
PHYSICAL REVIEW LETTERS
week ended
13 JANUARY 2012
Formation in Selenium-Hyperdoped Silicon: Observation and Origin
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Ertekin et al., Phys. Rev. Lett. 108, 026401 (2012)

1 properties

2 intermediate band

Emergence of very broad infrared absorption band by hyperdoping of silicon with chalcogens

JOURNAL OF APPLIED PHYSICS 113, 213501 (2013)

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We report the near through mid-infrared (MIR) optical absorption spectra, over the range 0.05–1.3 eV, of monocrystalline silicon layers hyperdoped with chalcogen atoms synthesized by ion implantation followed by pulsed laser melting. A broad mid-infrared optical absorption band emerges, peaking near 0.5 eV for sulfur and selenium and 0.3 eV for tellurium hyperdoped samples. Its strength and width increase with impurity concentration. Its strength decreases markedly with subsequent thermal annealing. The emergence of a broad MIR absorption band is consistent with the formation of an impurity band from isolated deep donor levels as the concentration of chalcogen atoms in metastable local configurations increases. © 2013 AIP Publishing LLC.
[http://dx.doi.org/10.1063/1.4804935]

I. INTRODUCTION

Silicon hyperdoped with chalcogens can be synthesized by pulsed laser irradiation in a sulfur-bearing atmosphere,^{1,2} ion implantation followed by pulsed laser melting,^{3,4} or pulsed laser mixing.⁵ This material has attracted interest because of its sub band gap absorption and has been studied as a candidate for infrared (IR) photodetectors^{6–8} and efficient solar cells.^{9–11} In addition, observations of carrier lifetime recovery for sufficiently high concentrations of titanium interstitials has aroused similar interest in this material.^{12,13} Hyperdoping has been shown to cause an intermediate bandgap and has been proposed to form an intermediate bandgap.^{4,10,14–16} However,

II. EXPERIMENT

Double side polished p type (001) Si wafers, resistivity of 5–25 Ω cm, were ion implanted at room temperature with either 95 keV ³²S[−], 176 keV ⁸⁰Se⁺, or 245 keV ¹³⁰Te⁺ to doses of 1×10^{16} ions/cm². The dose of ³²S[−] was varied from 3×10^{14} to 1×10^{16} ions/cm² and pre-amorphized by 85 keV Si[−] to doses of 3×10^{15} ions/cm² when the ³²S[−] dose is not greater than 1×10^{15} ions/cm². Pulsed laser melting was performed using a XeCl excimer laser beam (308 nm, 25 ns FWHM, 50 ns total duration). Each sample received three laser shots at 1.7 J/cm² followed by a fourth laser shot at 1.8 J/cm². Time-resolved reflectivity of a 488 nm Ar⁺ ion laser was used to measure the melt duration. The laser fluence was calibrated by comparing the melt duration with numerical solutions to the one-dimensional heat transfer equation.¹⁸ The details of the sample preparation method and the properties of the samples observed by secondary ion mass spectrometry are reported elsewhere.³ For samples, the procedure is the same

Emergence of very broad infrared absorption band by hyperdoping of silicon with chalcogens

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(Received October 1, 2012; accepted January 15, 2013)

We report the emergence of a very broad infrared absorption band in silicon implanted with chalcogen atoms.

The dose ranges from 0.05–1.3 × 10¹⁶ cm⁻².

Its strength increases with dose and its width decreases with dose.

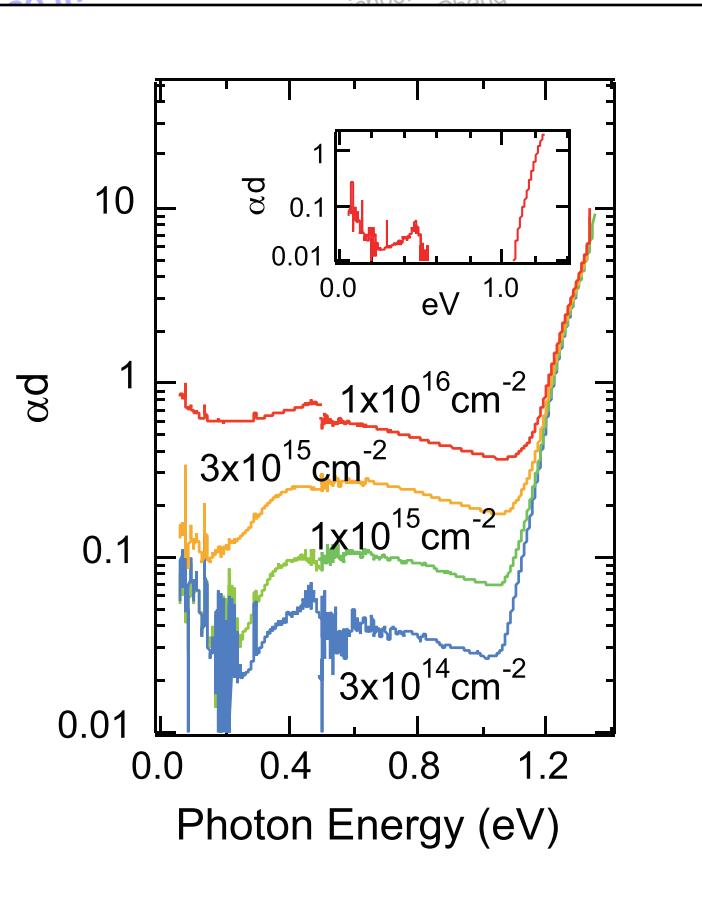
Its strength is proportional to the concentration of chalcogen atoms.

[http://dx.doi.org/10.1063/1.4787111]

I. INTRODUCTION

Silicon has been extensively studied as a material for photovoltaic applications by pulsed laser irradiation followed by pulsed laser annealing.^{1–4} This material has attracted attention because of its sub band gap absorption and has been studied as a candidate for infrared (IR) photodetectors^{6–8} and efficient solar cells.^{9,10} In addition, observations of carrier lifetime recovery for sufficient hyperdoping have been shown to cause an intermediate bandgap.^{11–13} Hyperdoping has been proposed to form an intermediate bandgap.^{14–16} However,

hyperdoped p type (001) Si wafers, resistivity on implanted at room temperature with 176 keV ⁸⁰Se⁺, or 245 keV ¹³⁰Te⁺ to 1.3 × 10¹⁶ ions/cm². The dose of ³²S[−] was varied to doses of 3 × 10¹⁵ ions/cm² when the ³²S[−] dose is not greater than 1 × 10¹⁵ ions/cm². Pulsed laser melting was performed using a XeCl excimer laser beam (308 nm, 25 ns FWHM, 50 ns total duration). Each sample received three laser shots at 1.7 J/cm² followed by a fourth laser shot at 1.8 J/cm². Time-resolved reflectivity of a 488 nm Ar⁺ ion laser was used to measure the melt duration. The laser fluence was calibrated by comparing the melt duration with numerical solutions to the one-dimensional heat transfer equation.¹⁷ The details of the sample preparation method and characterization procedures are reported elsewhere.³ For samples, the procedure is the same



Umezu et al., J. Appl. Phys. 113, 213501 (2013)

1 properties

2 intermediate band

Understanding the Viability of Impurity-Band Photovoltaics: A Case Study of S-doped Si

by

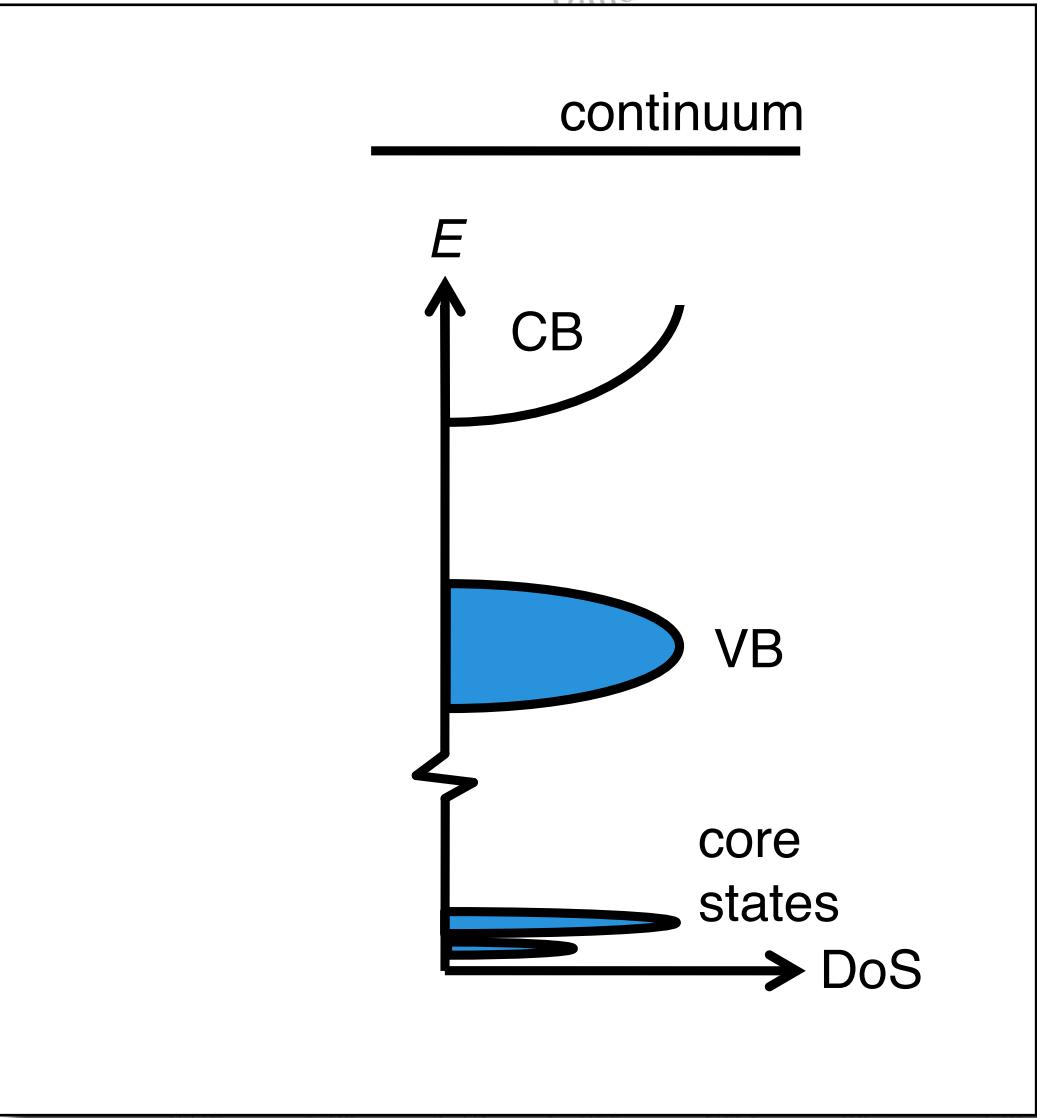
Joseph Timothy Sullivan

Submitted to the Department of Mechanical Engineering
on May 18, 2013, in partial fulfillment of the
requirements for the degree of
Doctor of Philosophy

Abstract

This thesis explores the electronic structure, optical properties, and carrier lifetimes in silicon that is doped with sulfur beyond the equilibrium solid solubility limit, with a focus on applications as an absorber layer for an impurity-band photovoltaic device. The concept of an impurity-band material envisions the creation of a band of electronic states by incorporating high concentrations of deep-level dopants, which enable the generation of free carriers using photons with energy less than that of the band gap of the host semiconductor. The investigations reported in this thesis provide a framework for the appropriate selection of impurity-band candidate materials. The thesis is divided into three primary sections, one for each of three experimental techniques, respectively.

First, the electronic band structure is studied using synchrotron-based x-ray emission spectroscopy. These spectra provide the first insights into how the electronic structure changes as the sulfur concentration is increased across the metal-insulator transition, and how the electronic structure is linked to the anomalously high sub-band gap absorption. A discrete change in local electronic structure is seen that corresponds to the macroscopic change in electronic behavior. Additionally, a direct correlation is seen between sulfur-induced states and the sub-band gap absorption. The optical properties are studied using Fourier transform infrared spectroscopy, and the variation of the complex index of refraction is performed using numerical transmission and reflection measurements. Analysis of the position of the sulfur-induced states within the metal-insulator transition, different sulfur concentrations and the position of the sulfur-induced transition band,

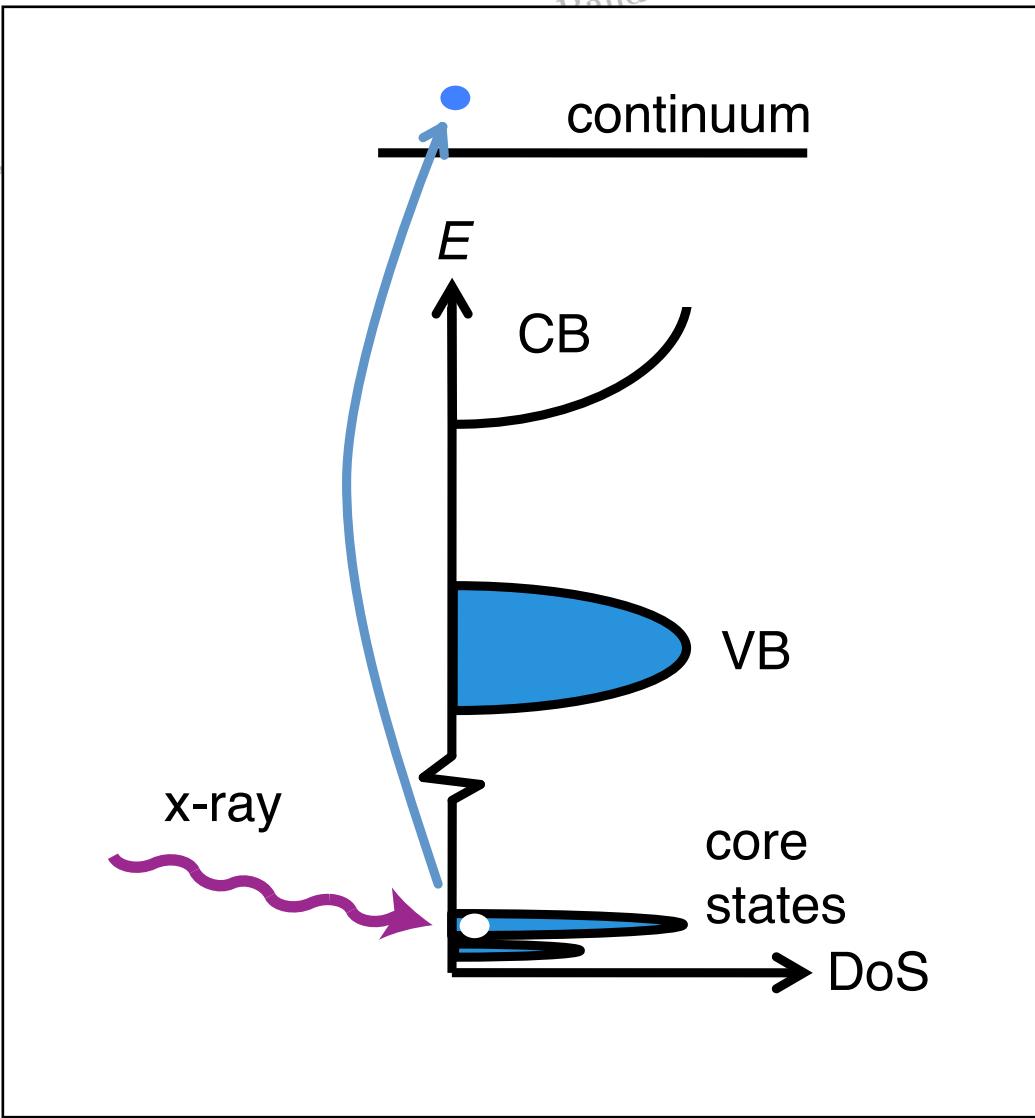


J. Sullivan, Ph.D. Thesis, MIT (2013)

1 properties

2 intermediate band

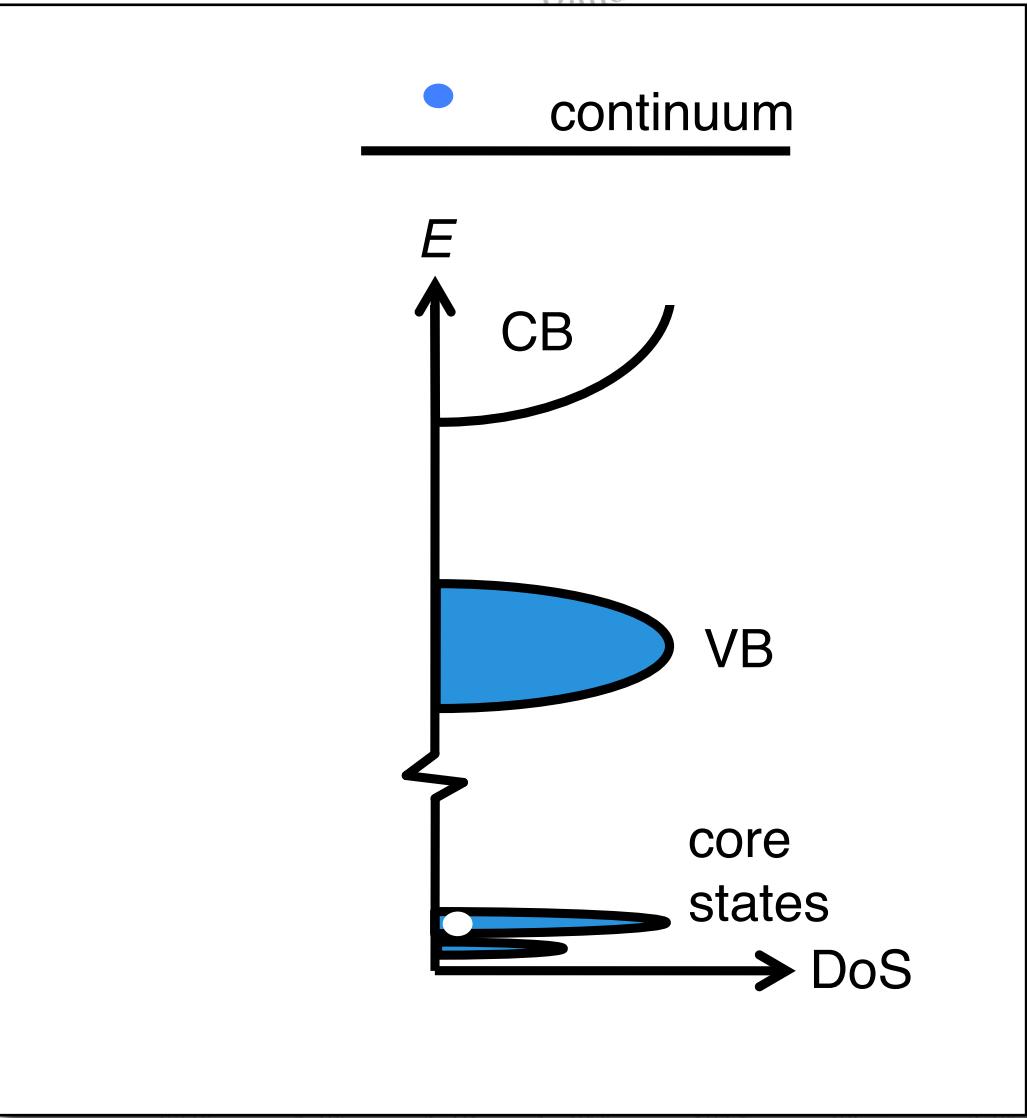
Understand
Band Photovoltaics:



J. Sullivan, Ph.D. Thesis, MIT (2013)

1 properties

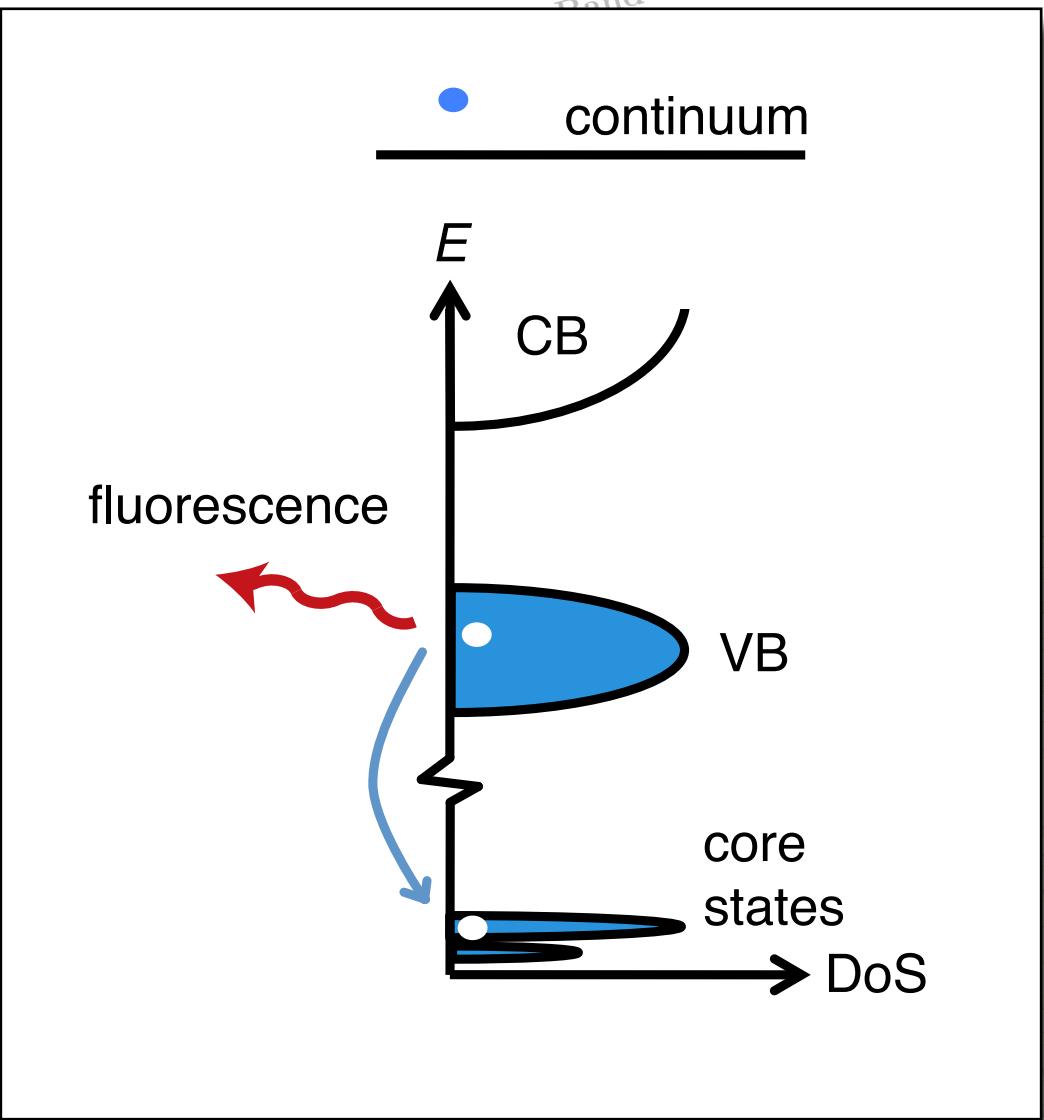
2 intermediate band



J. Sullivan, Ph.D. Thesis, MIT (2013)

1 properties

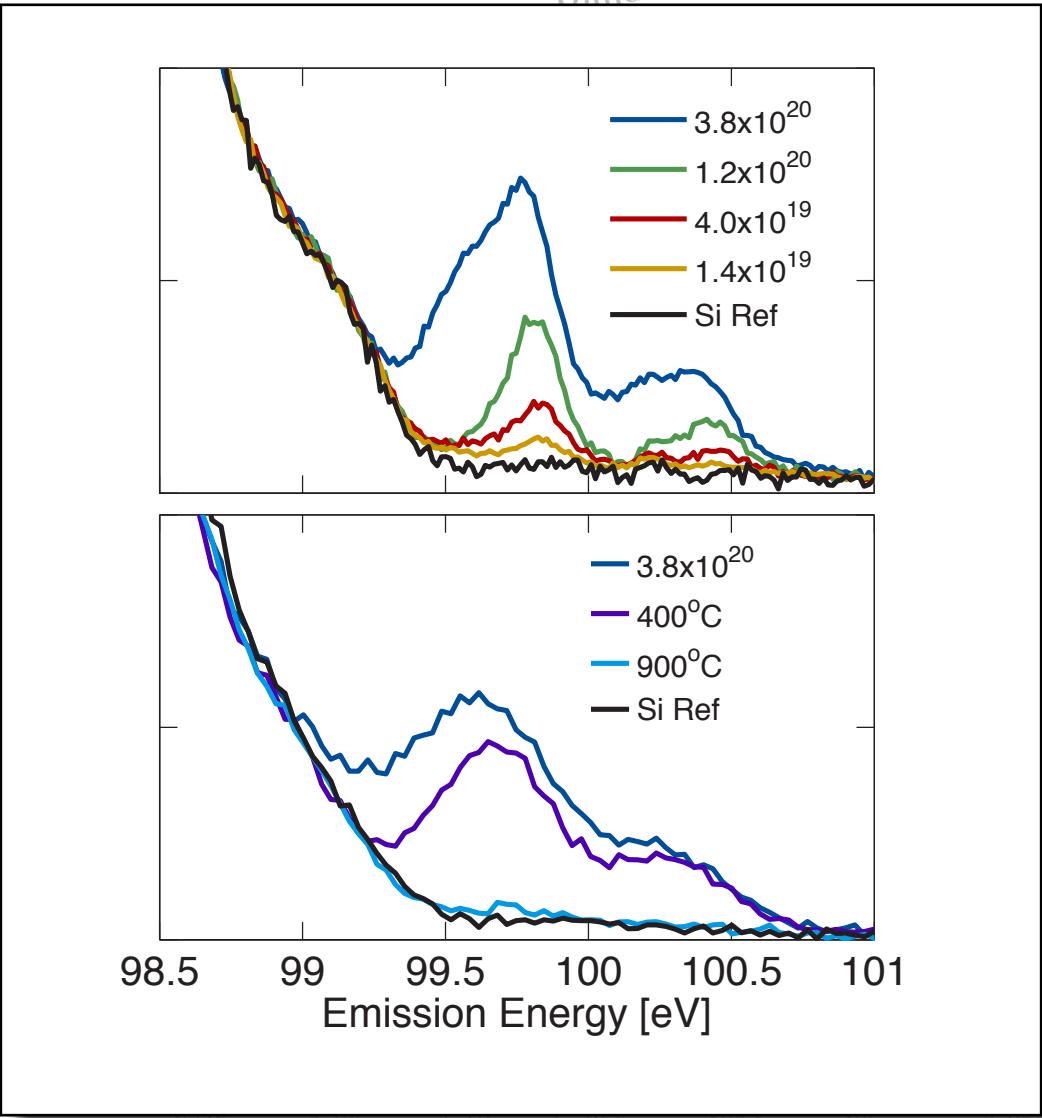
2 intermediate band



J. Sullivan, Ph.D. Thesis, MIT (2013)

1 properties

2 intermediate band



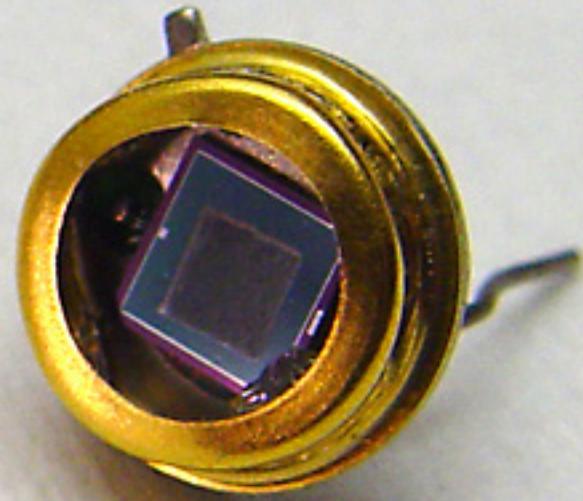
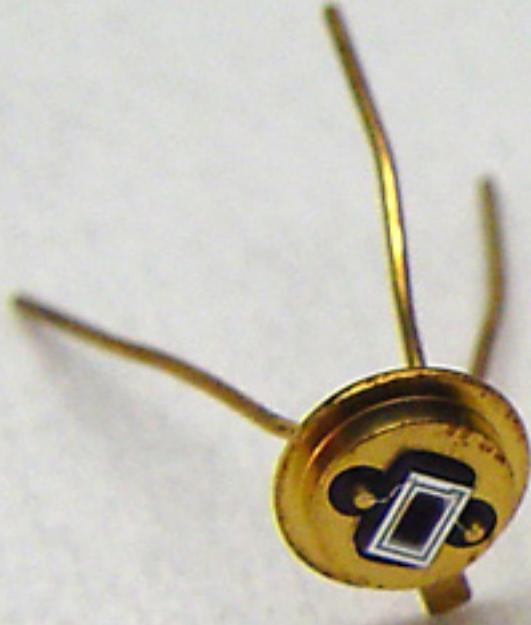
J. Sullivan, Ph.D. Thesis, MIT (2013)

1 properties

2 intermediate band

Things to keep in mind

- IR absorption rolls off around $8 \mu\text{m}$
- consistent evidence of intermediate band formation
- IB forms at 0.1% at. doping, broadens at higher doping
- IB merges with CB at 0.4% at. yielding metallic behavior

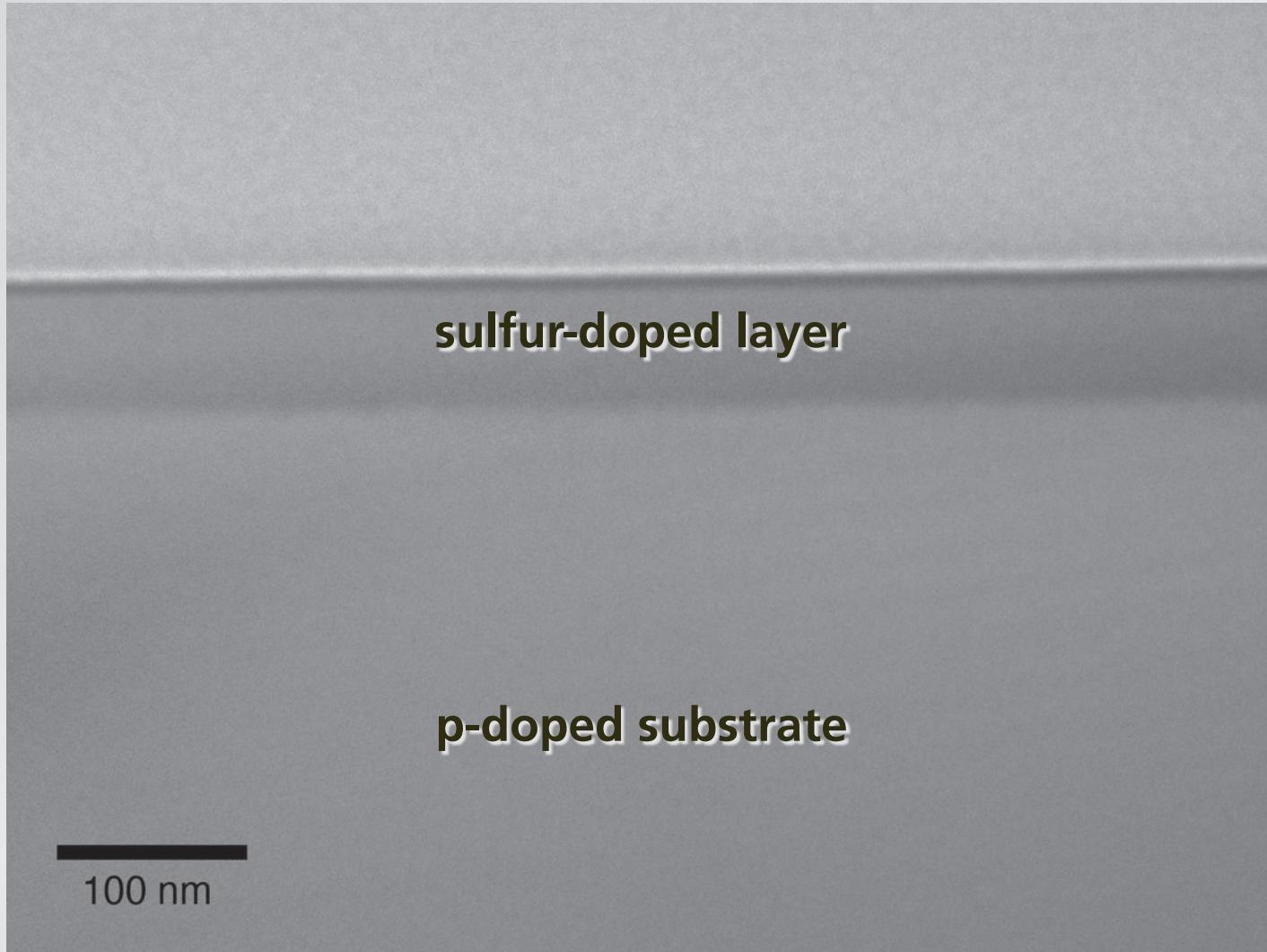


1 properties

2 intermediate band

3 devices

should have shallow junction below surface

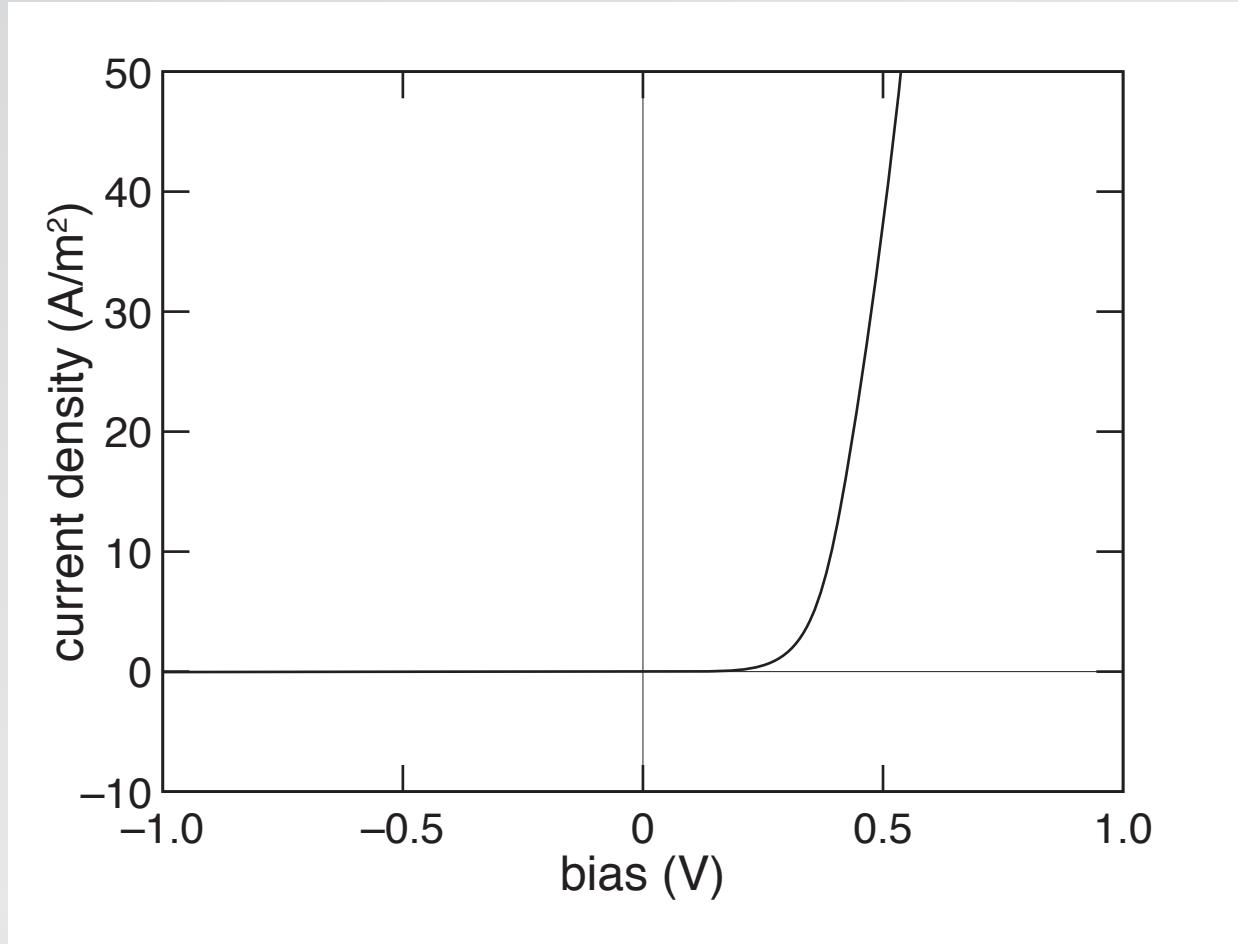


1 properties

2 intermediate band

3 devices

excellent rectification (after annealing)

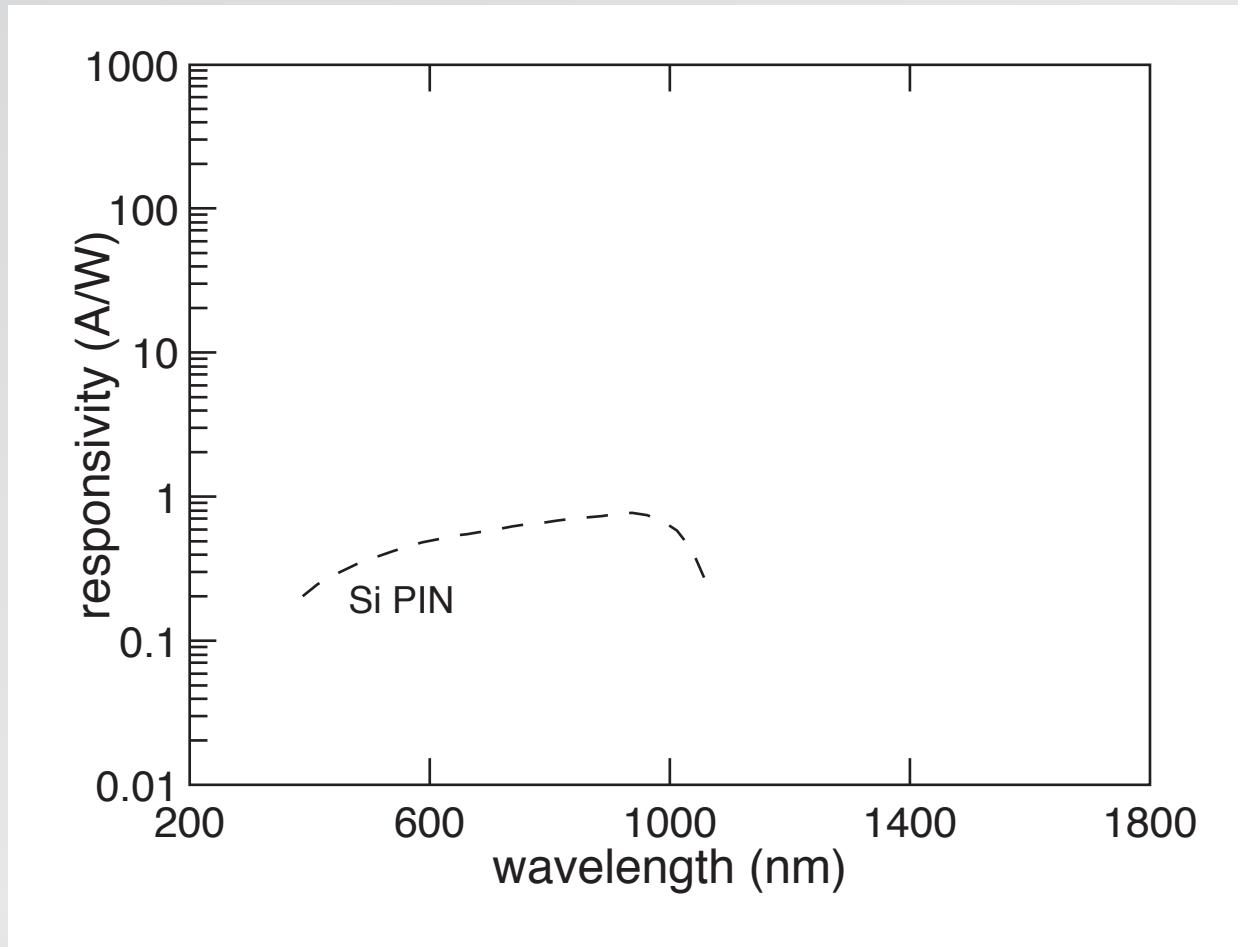


1 properties

2 intermediate band

3 devices

responsivity

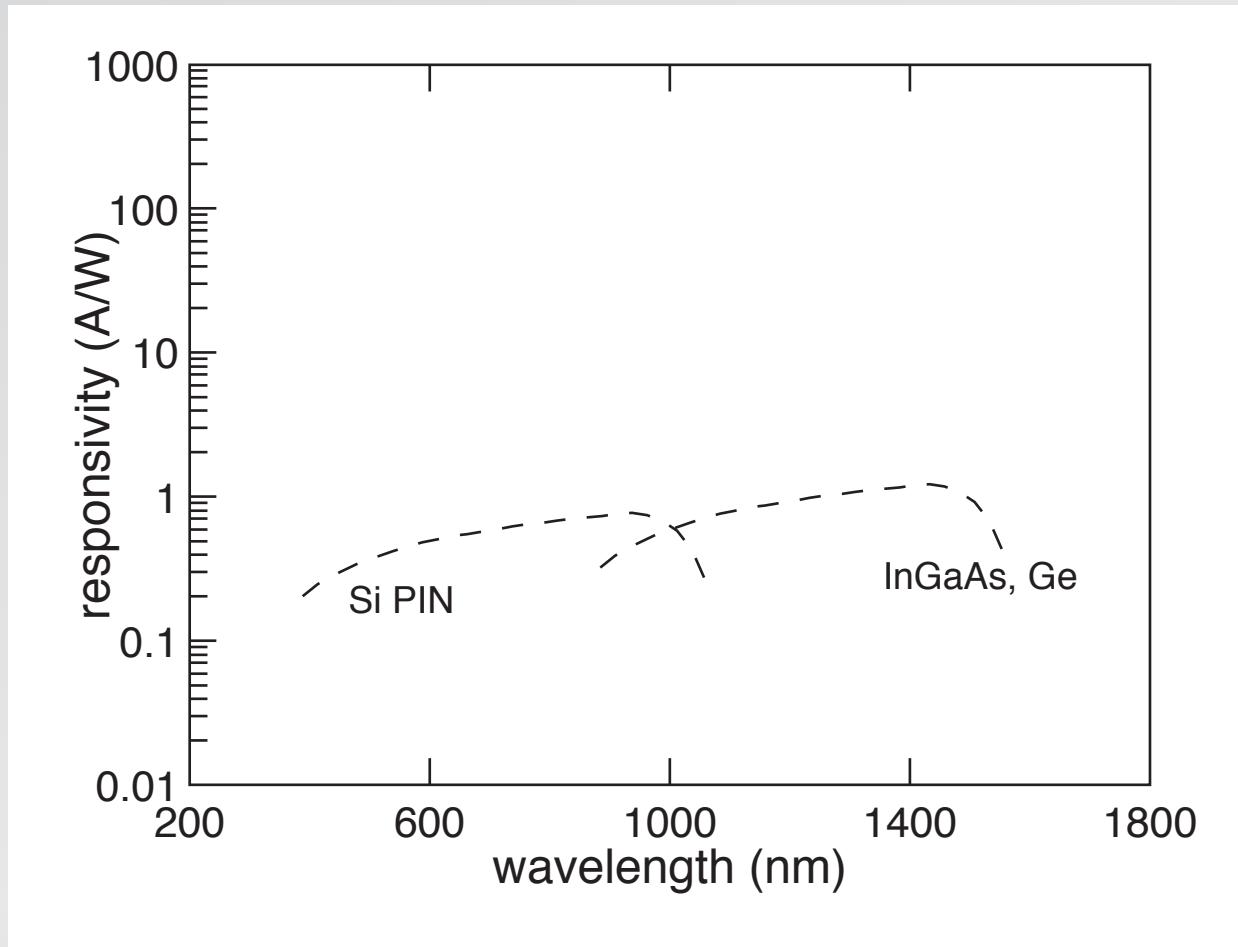


1 properties

2 intermediate band

3 devices

responsivity

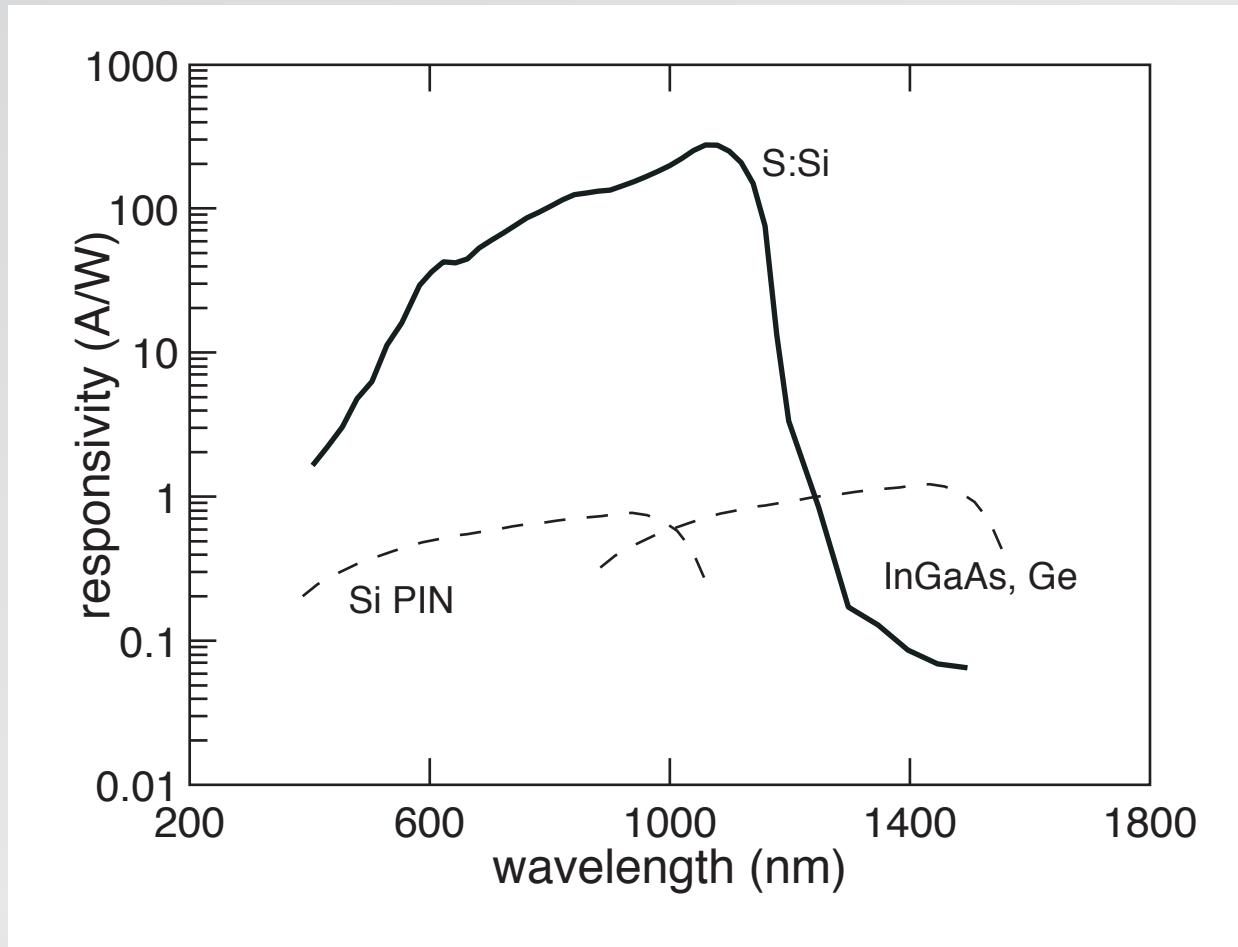


1 properties

2 intermediate band

3 devices

responsivity

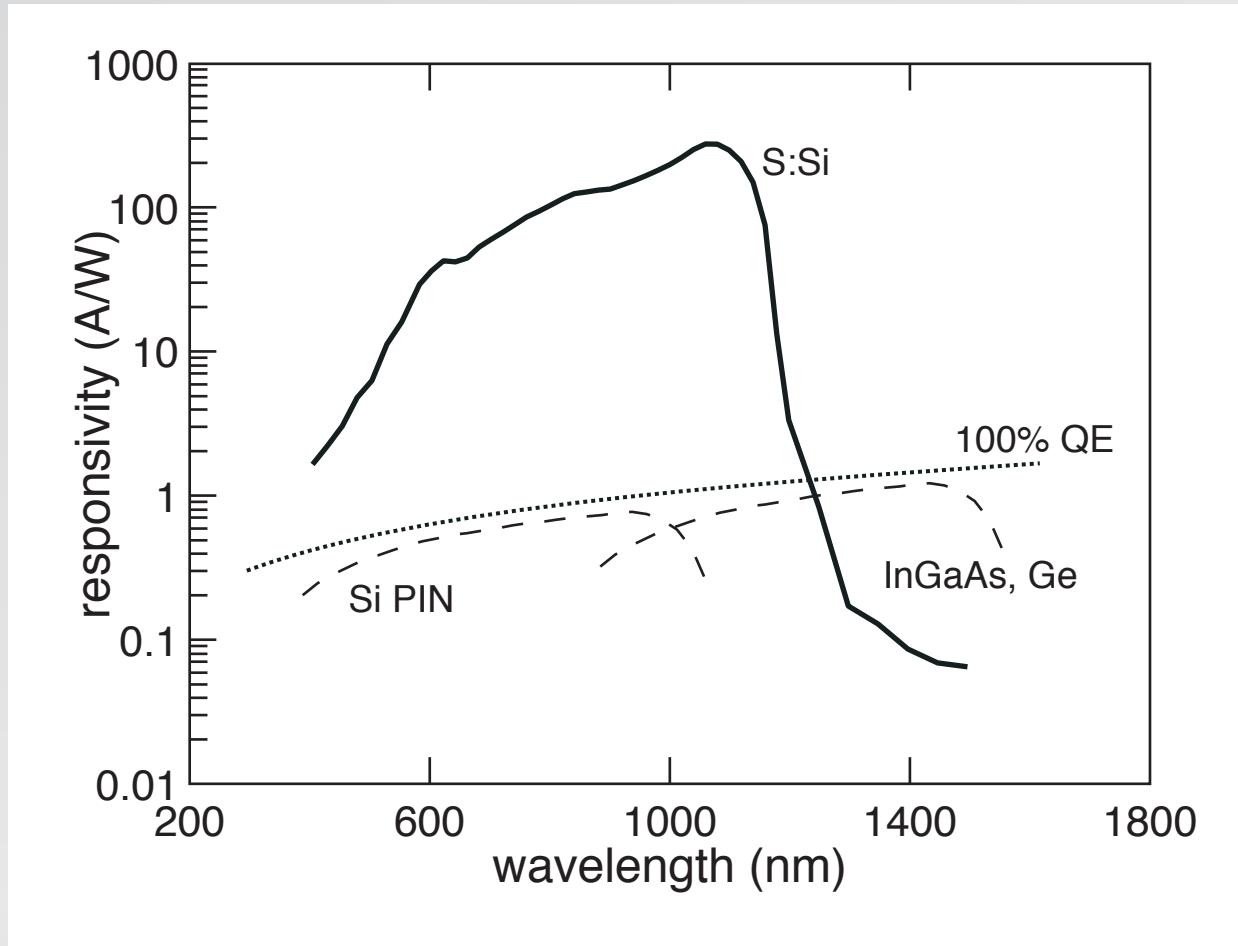


1 properties

2 intermediate band

3 devices

responsivity

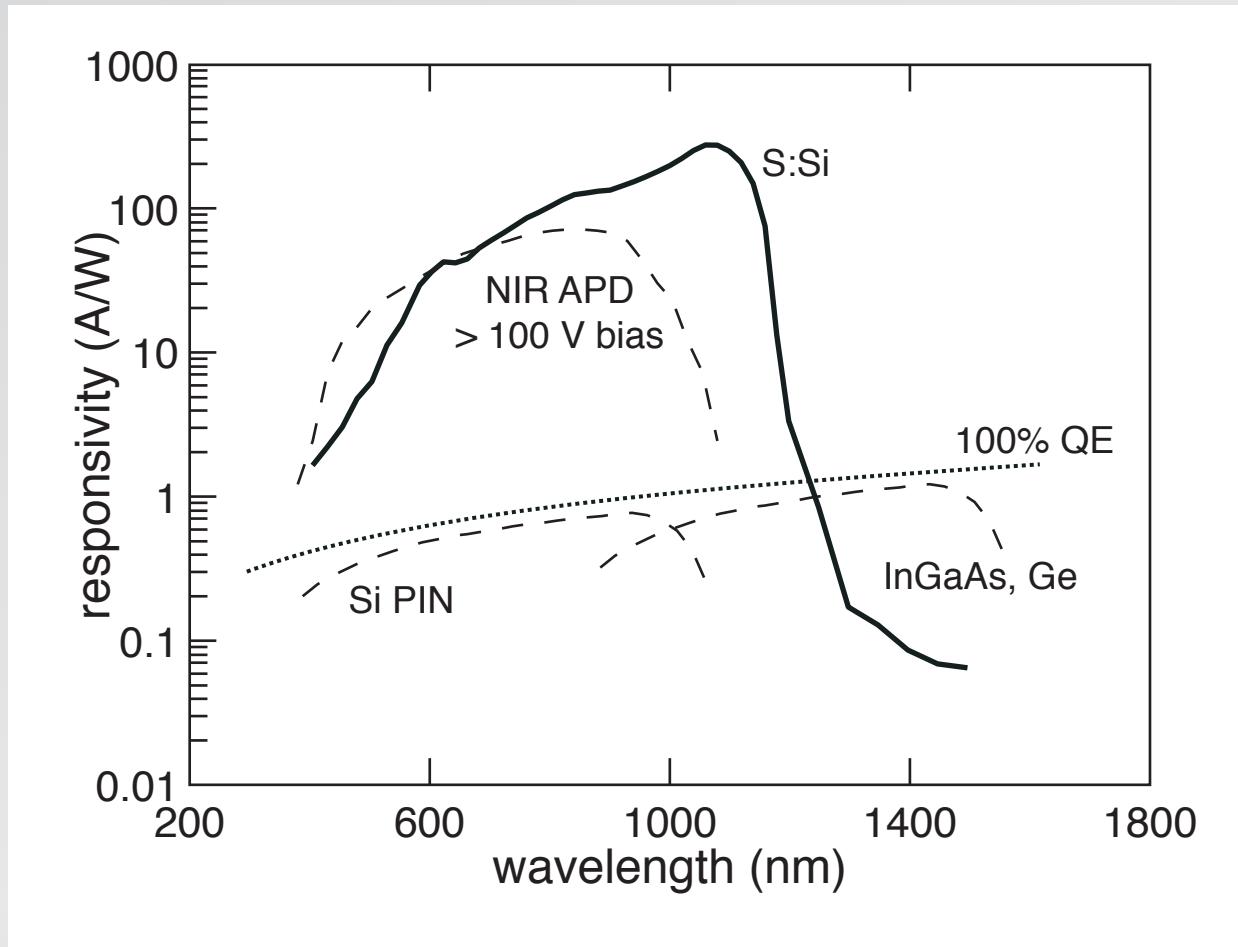


1 properties

2 intermediate band

3 devices

responsivity



1 properties

2 intermediate band

3 devices

- enhanced sensitivity
- extended IR response

1 properties

2 intermediate band

3 devices

near-IR is next wave in imaging!

1 properties

2 intermediate band

3 devices



gesture recognition

image: fastcolabs.com

1 properties

2 intermediate band

3 devices

A night vision photograph of a person standing in a field. The person is wearing a dark jacket and pants, and appears to be holding a rifle. The background shows a grassy field with some trees in the distance. The image has a greenish tint characteristic of night vision cameras.

night vision

wikimedia.org

1 properties

2 intermediate band

3 devices

biometrics

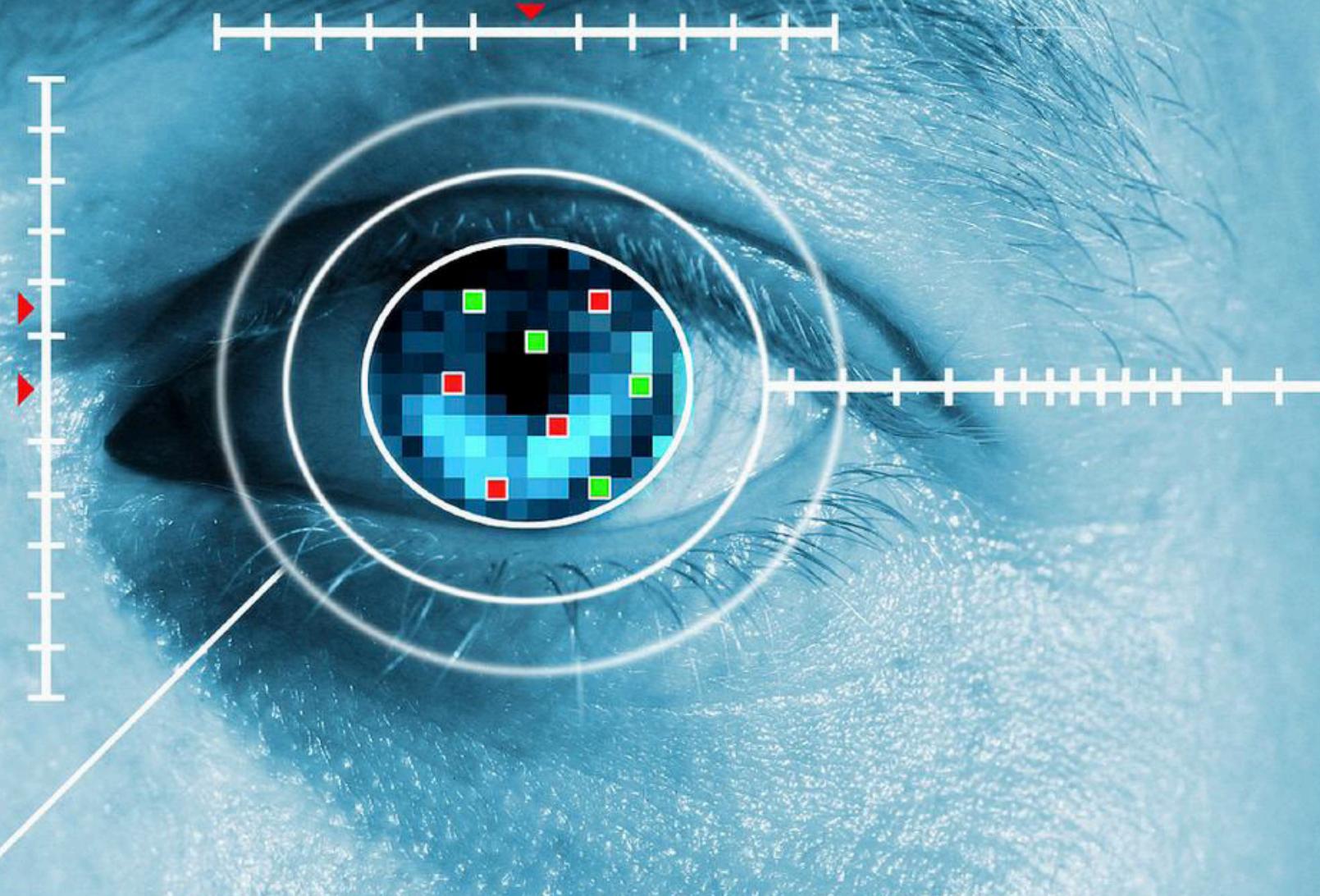


image: kusic.ca

1 properties

2 intermediate band

3 devices

robotics

image: AP images

1 properties

2 intermediate band

3 devices



www.sionyx.com



1 properties

2 intermediate band

3 devices

**Combine state-of-the-art low-noise CMOS image
sensor design with enhanced quantum efficiency**



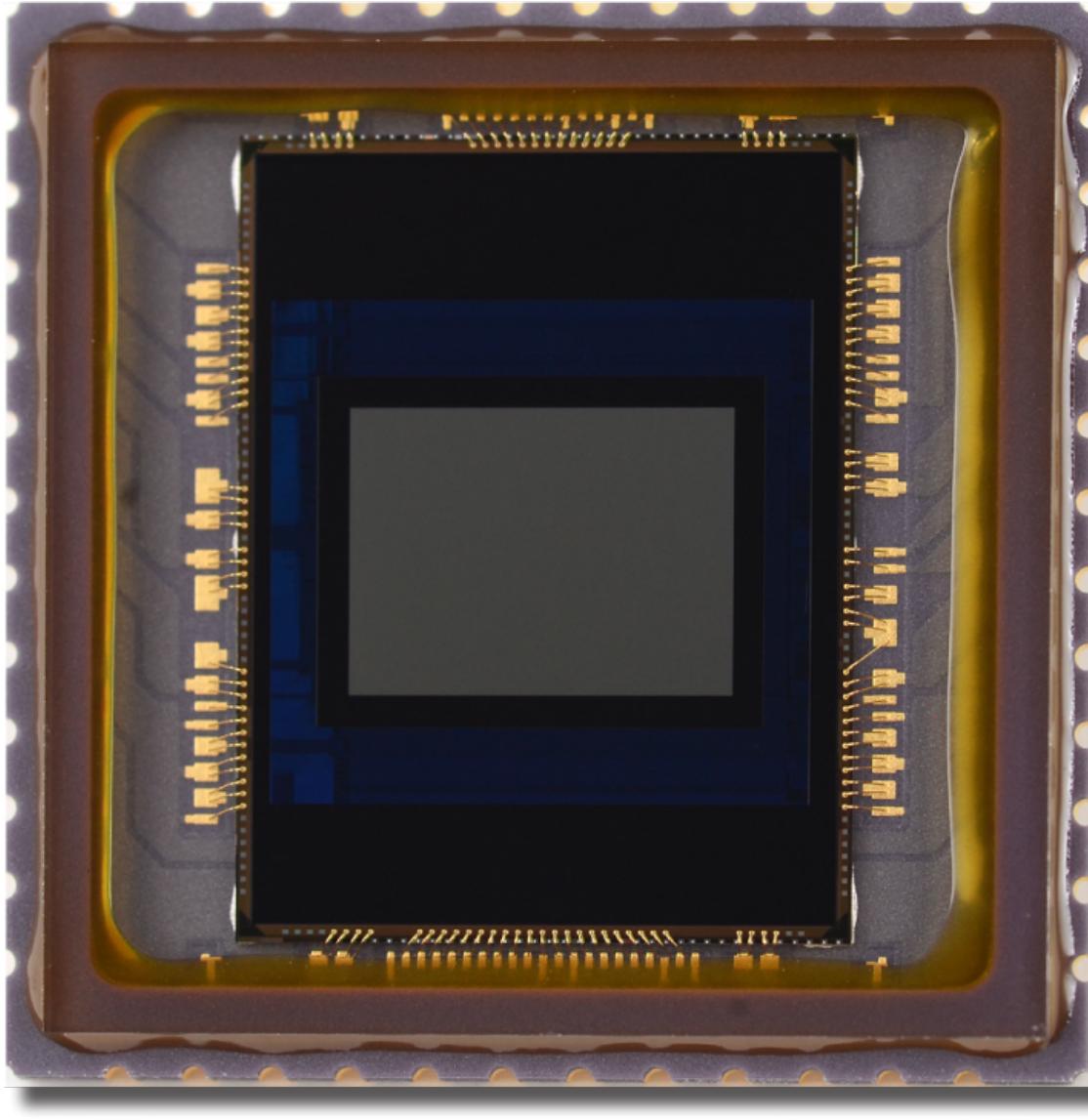
SiOnyx

US Patents: US 8,058,615; US 7,928,355; US 7,968,834

1 properties

2 intermediate band

3 devices

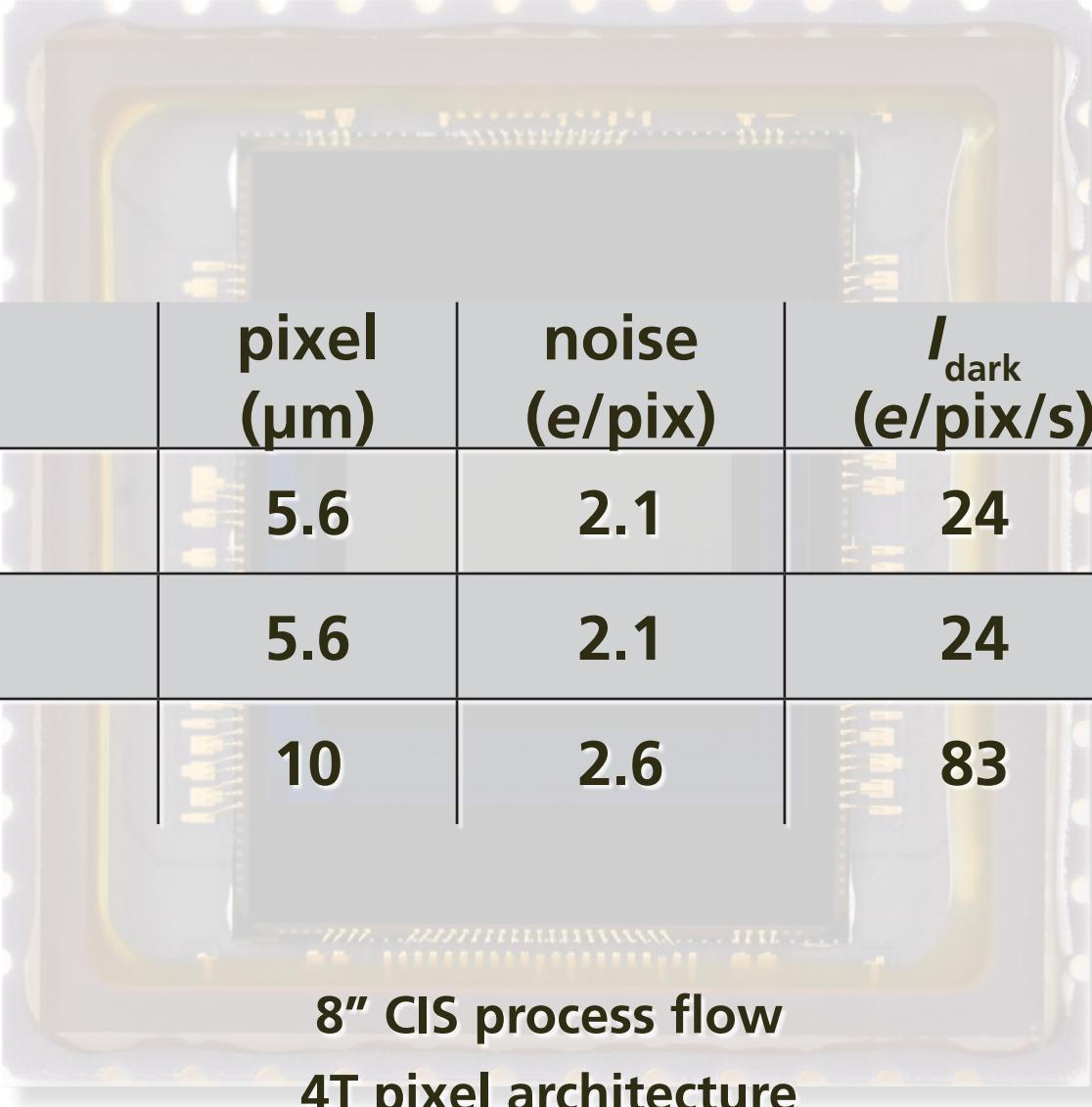


US Patents: US 8,058,615; US 7,928,355; US 7,968,834

1 properties

2 intermediate band

3 devices



8" CIS process flow
4T pixel architecture

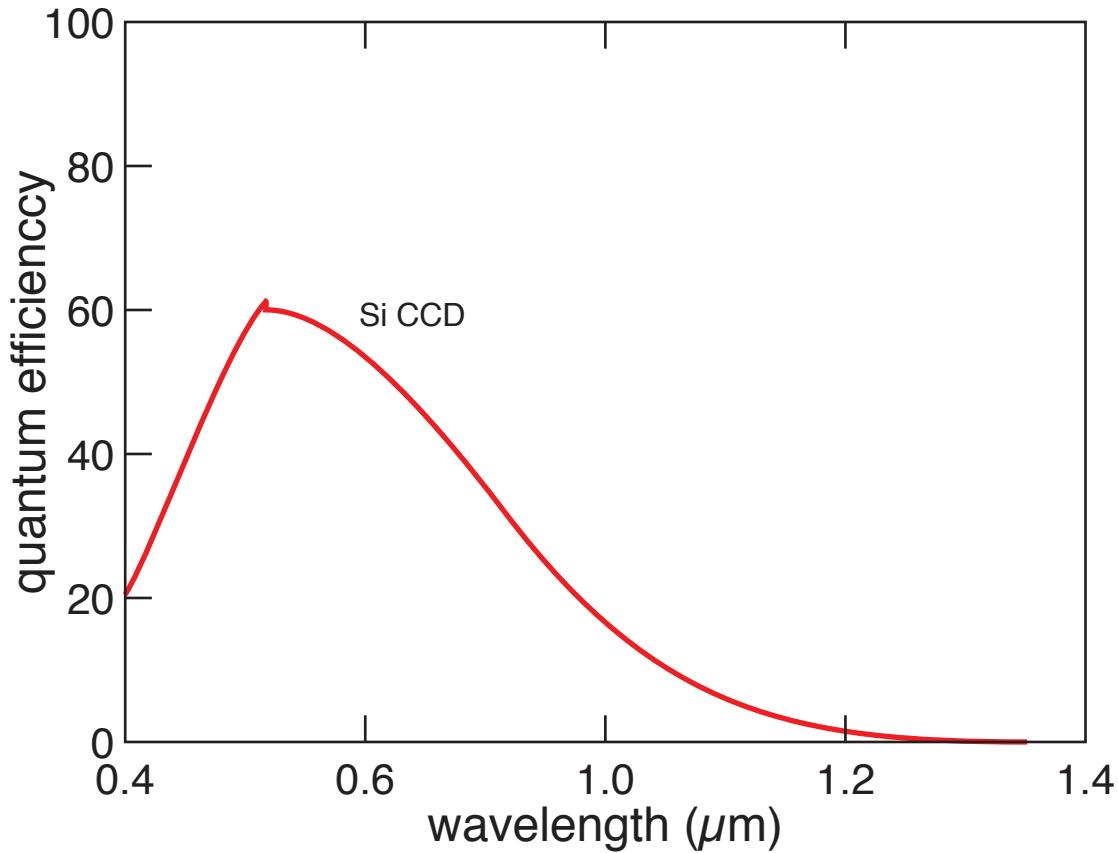
Resolution	pixel (μm)	noise (e/pix)	I_{dark} (e/pix/s)	P (mW)
872 x 654	5.6	2.1	24	300
1280 x 720	5.6	2.1	24	360
1280 x 1024	10	2.6	83	400



1 properties

2 intermediate band

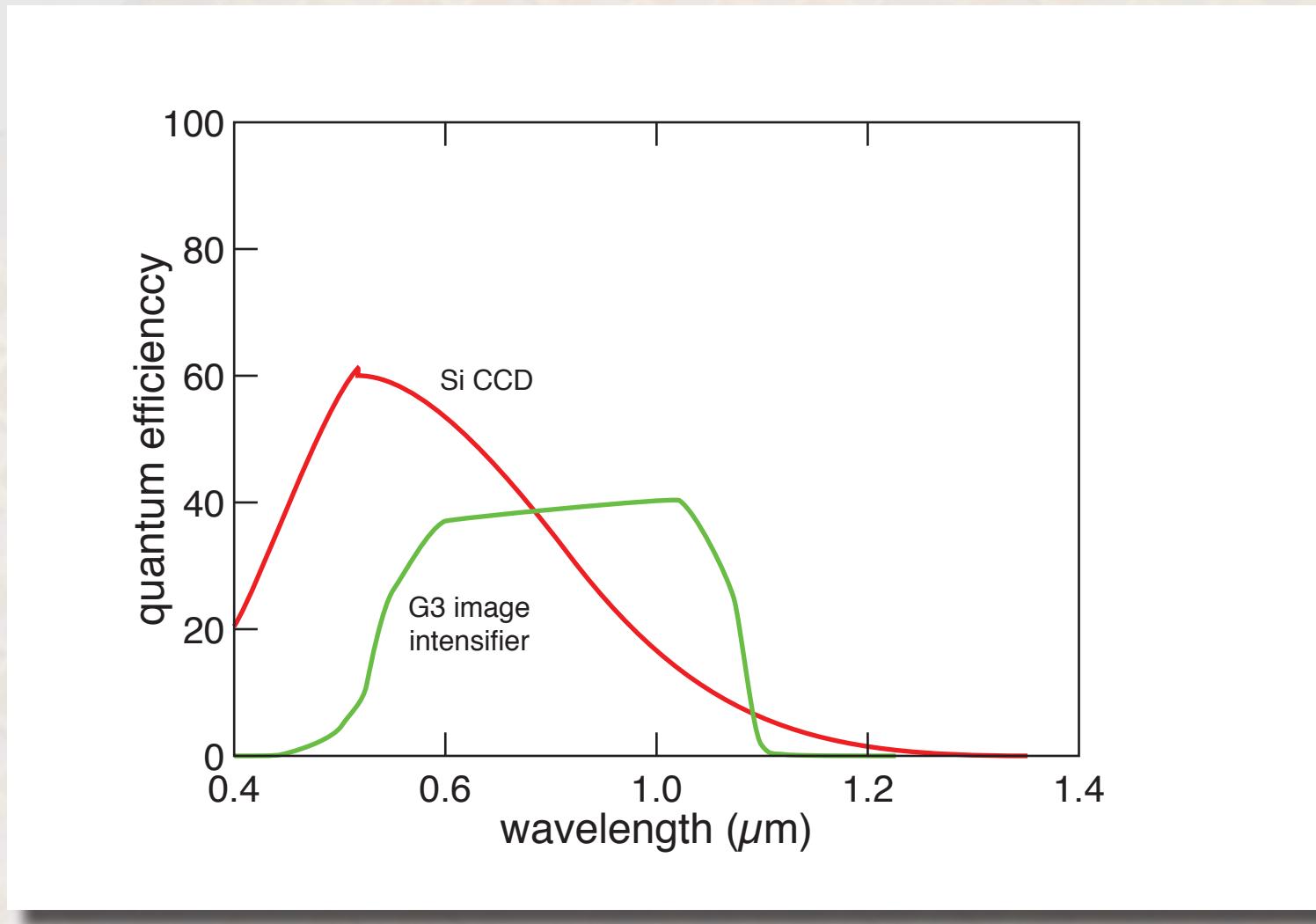
3 devices



1 properties

2 intermediate band

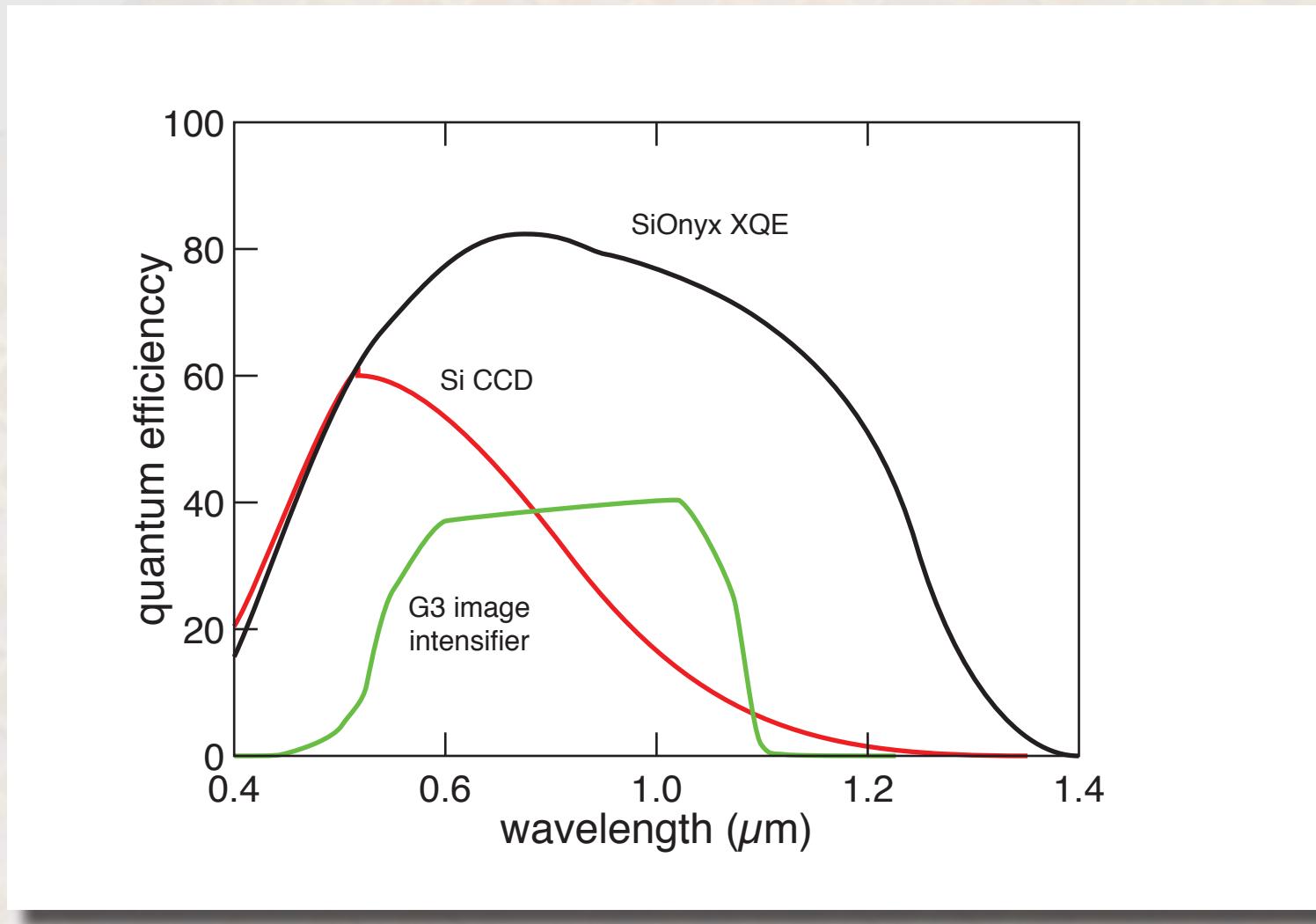
3 devices



1 properties

2 intermediate band

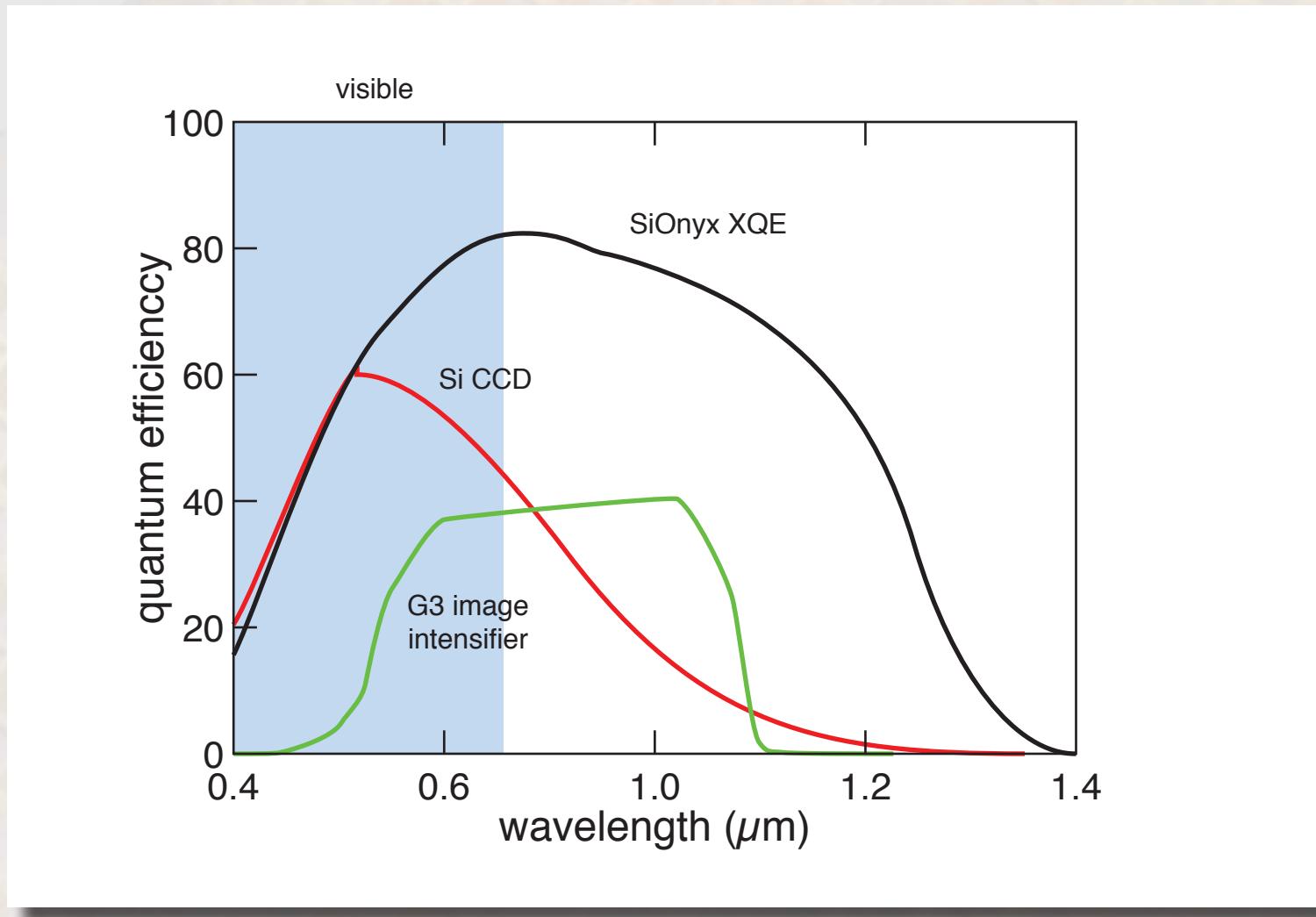
3 devices



1 properties

2 intermediate band

3 devices



1 properties

2 intermediate band

3 devices

no compromises in visible



Sony color CCD



1 properties

2 intermediate band

3 devices

no compromises in visible



Sony color CCD



SiOnyx XQE sensor



1 properties

2 intermediate band

3 devices

90+ dB dynamic range



Sony color CCD

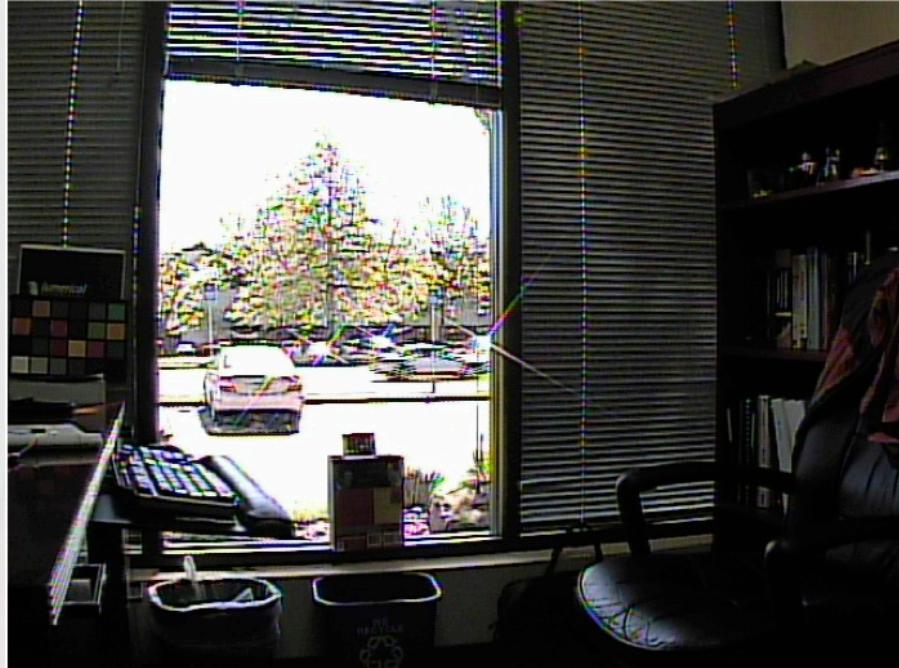


1 properties

2 intermediate band

3 devices

90+ dB dynamic range



Sony color CCD



SiOnyx X1 sensor

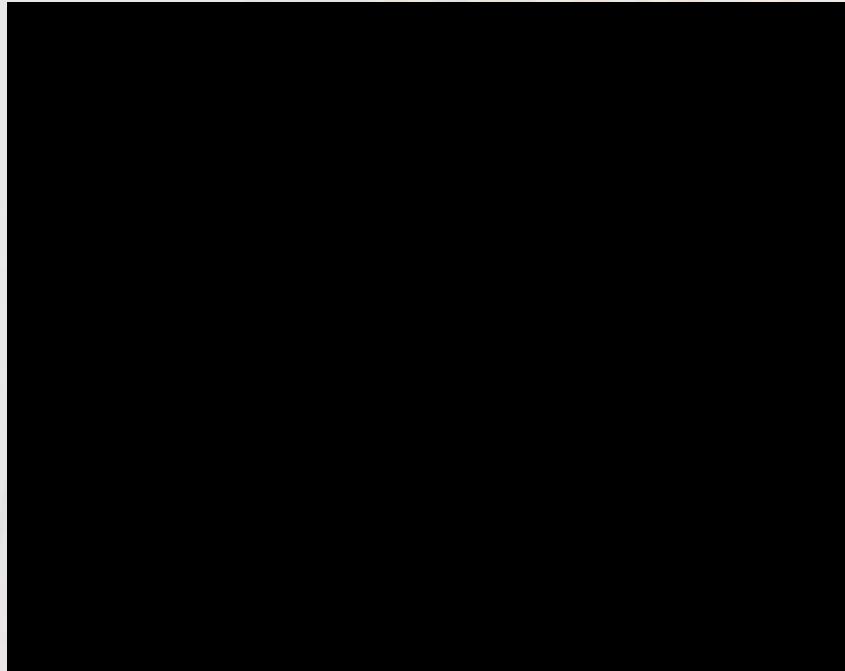


1 properties

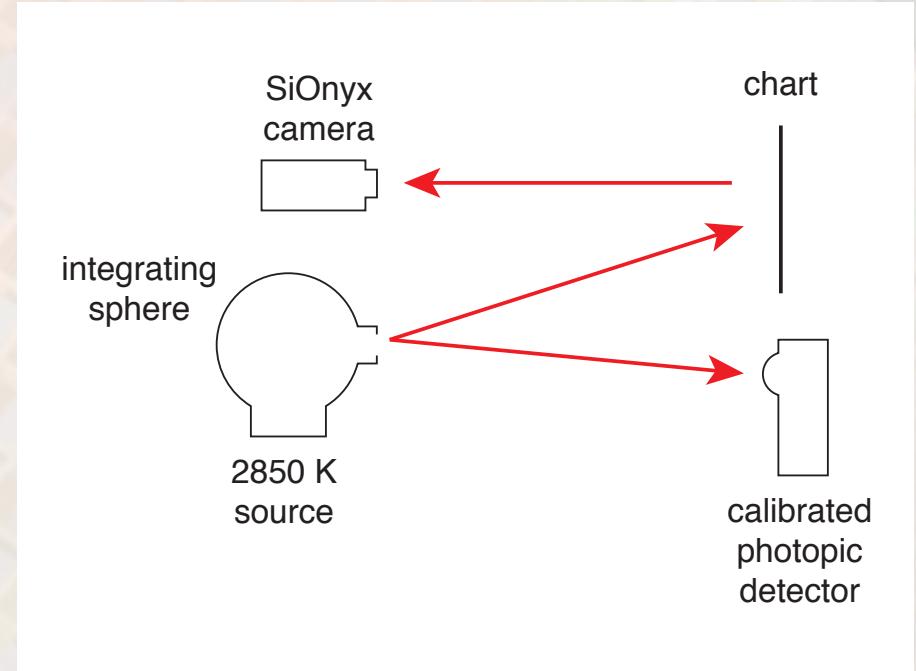
2 intermediate band

3 devices

0.9 mlx irradiance from 2850 K source



SiOnyx (50 mm, F1.4, 30 fps)

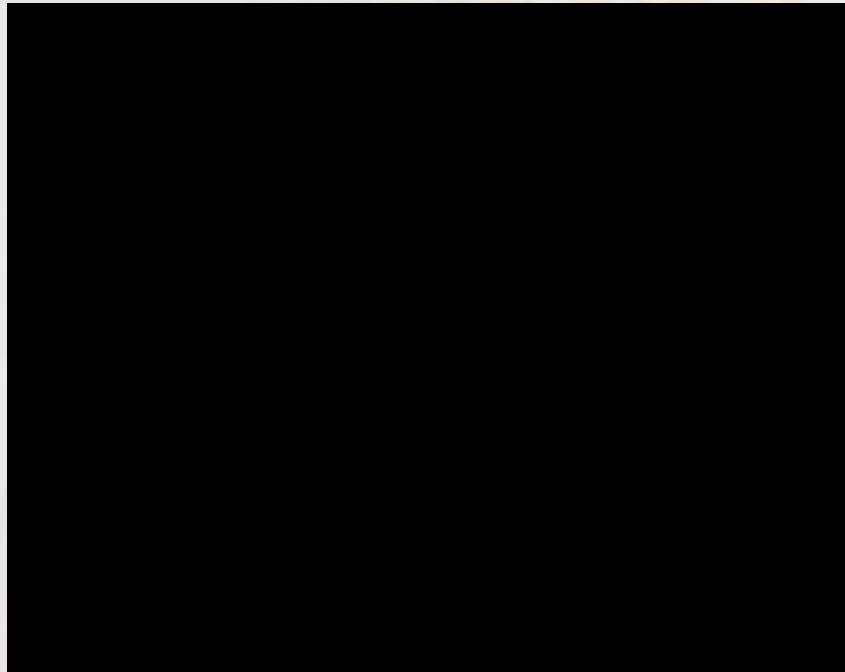


1 properties

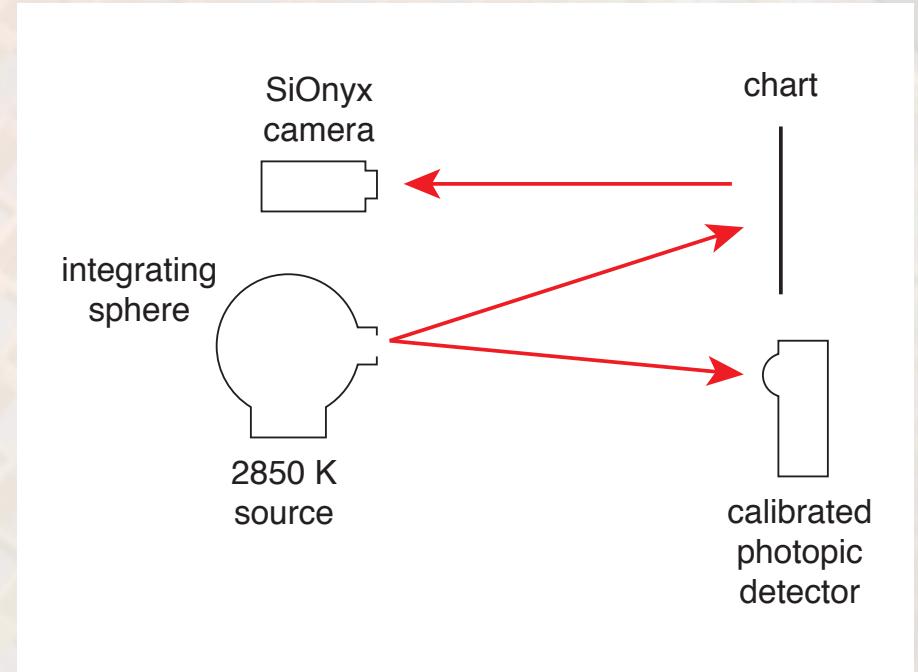
2 intermediate band

3 devices

0.9 mlx irradiance from 2850 K source



SiOnyx (50 mm, F1.4, 60 fps)

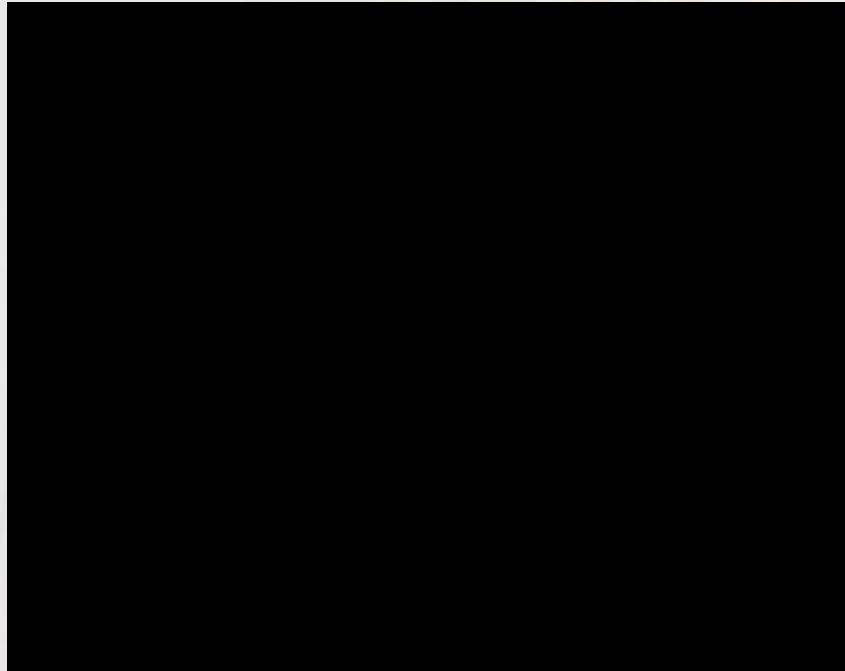


1 properties

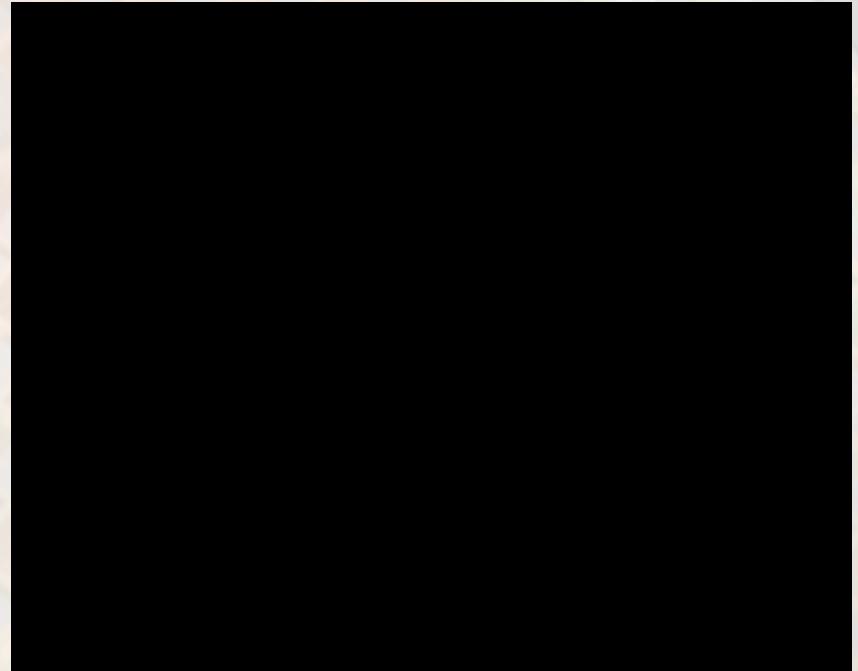
2 intermediate band

3 devices

0.9 mlx irradiance from 2850 K source



SiOnyx (50 mm, F1.4, 60 fps)



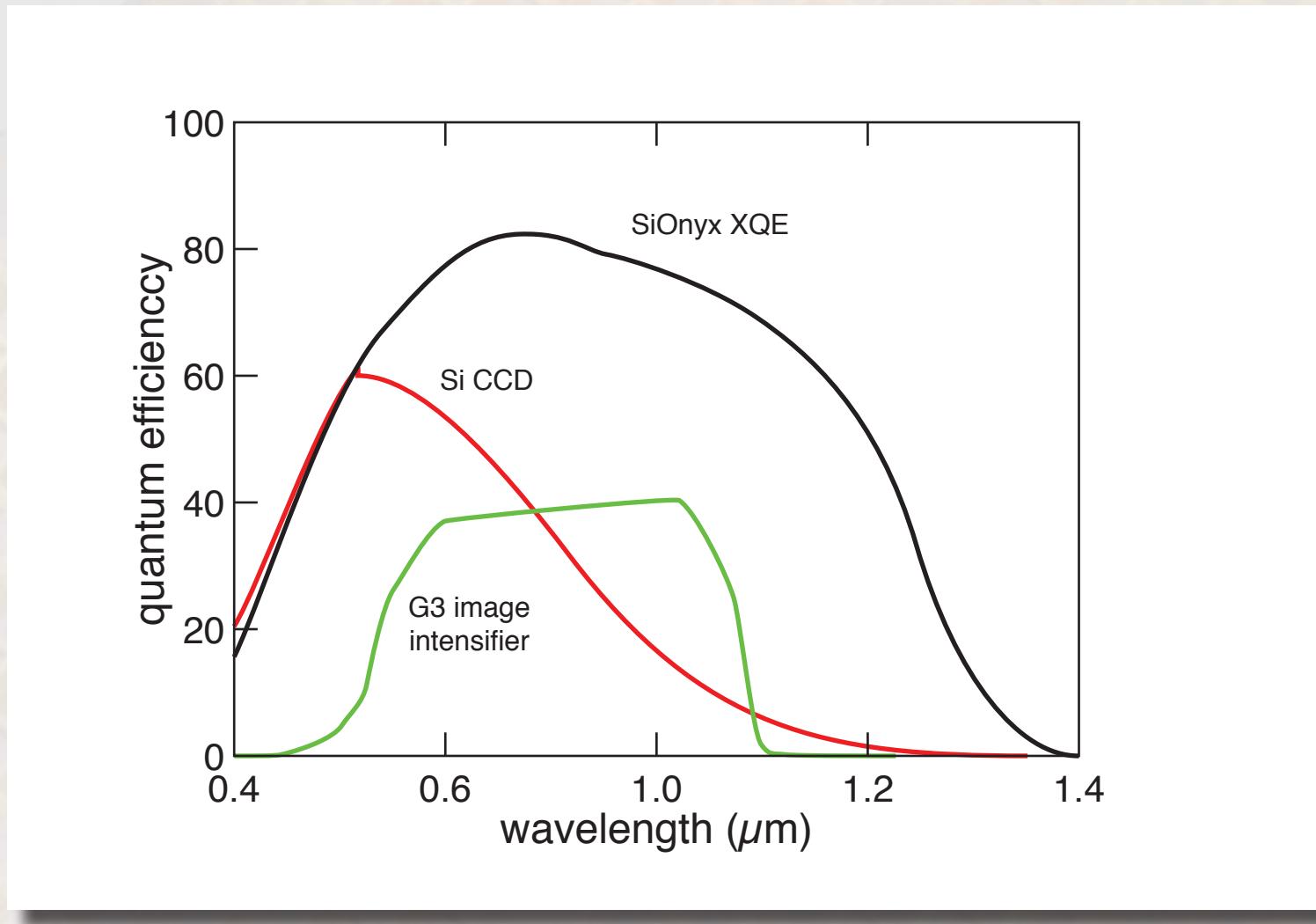
CCD (8 mm, F1.4, 60 fps)



1 properties

2 intermediate band

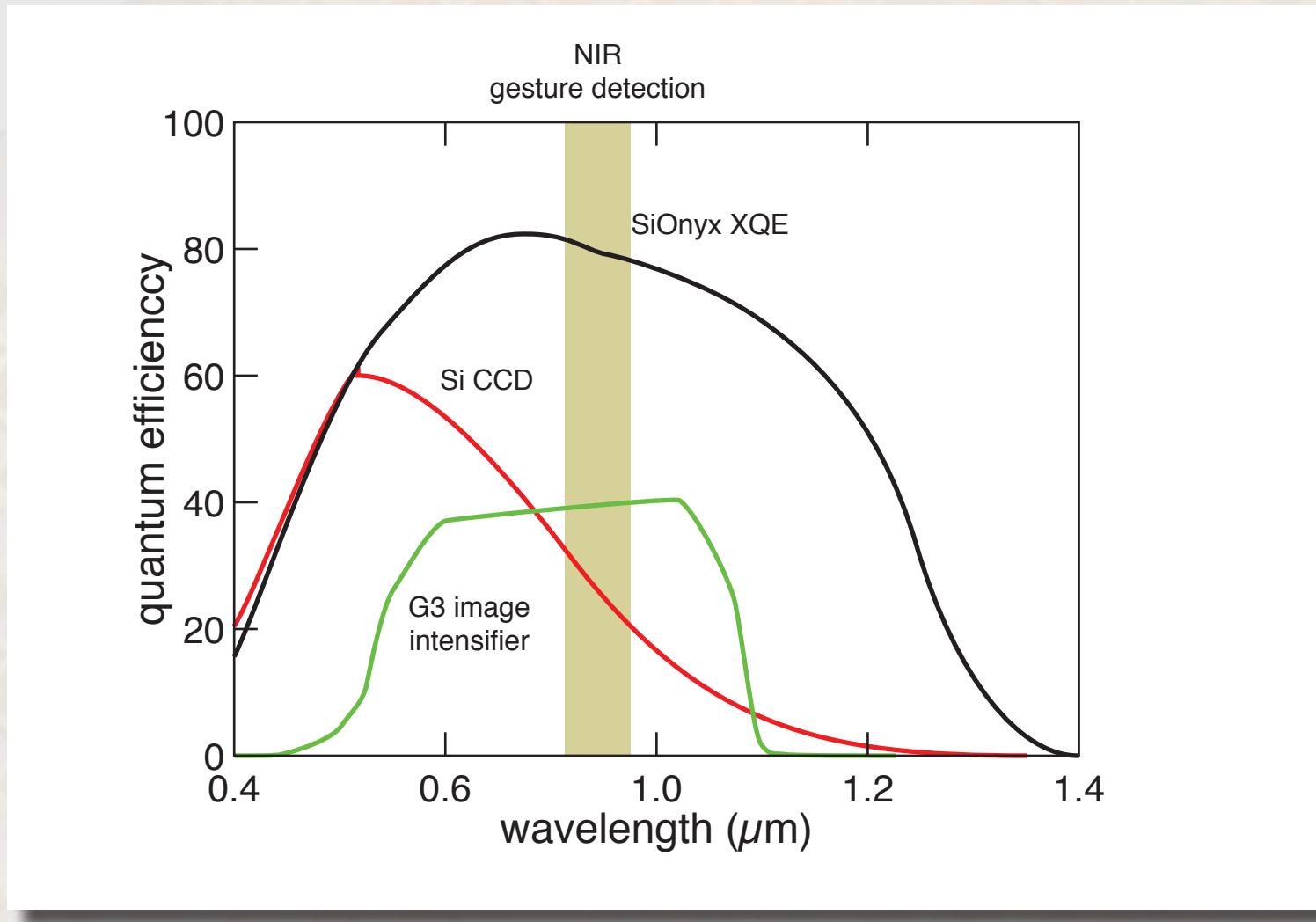
3 devices



1 properties

2 intermediate band

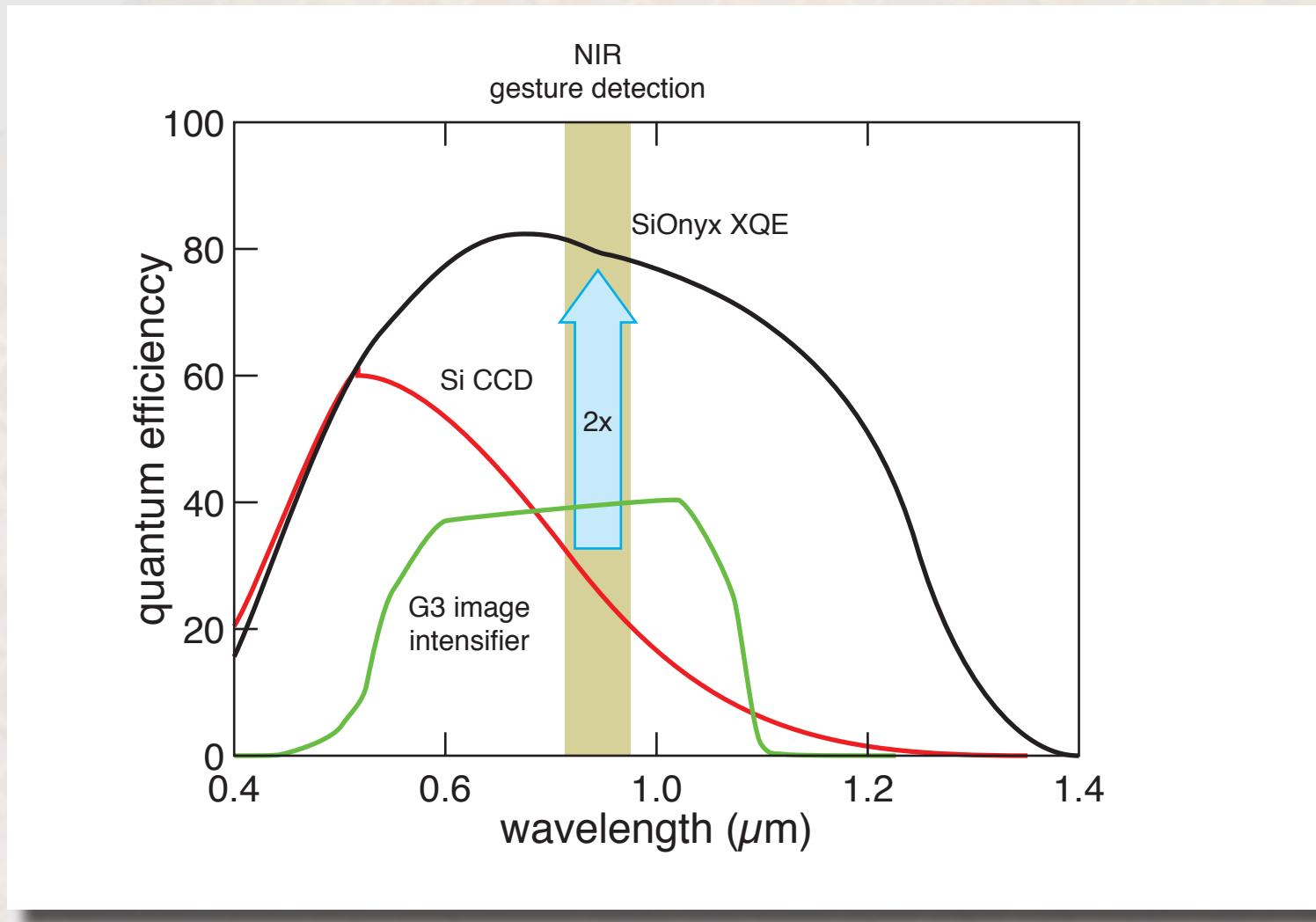
3 devices



1 properties

2 intermediate band

3 devices



1 properties

2 intermediate band

3 devices

3D imaging for gesture user interface (850 nm)



SiOnyx XQE



standard CCD

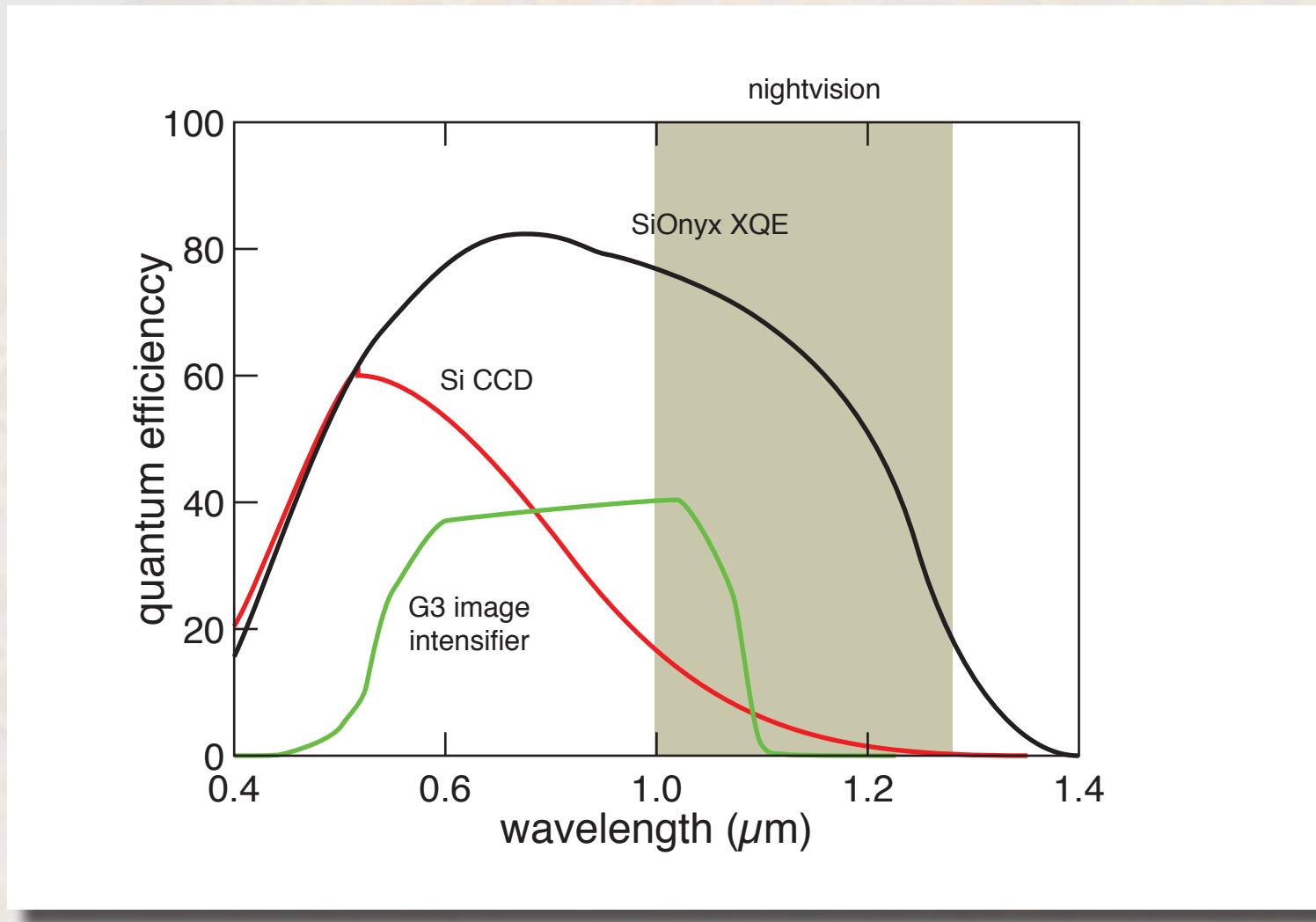


SiOnyx

1 properties

2 intermediate band

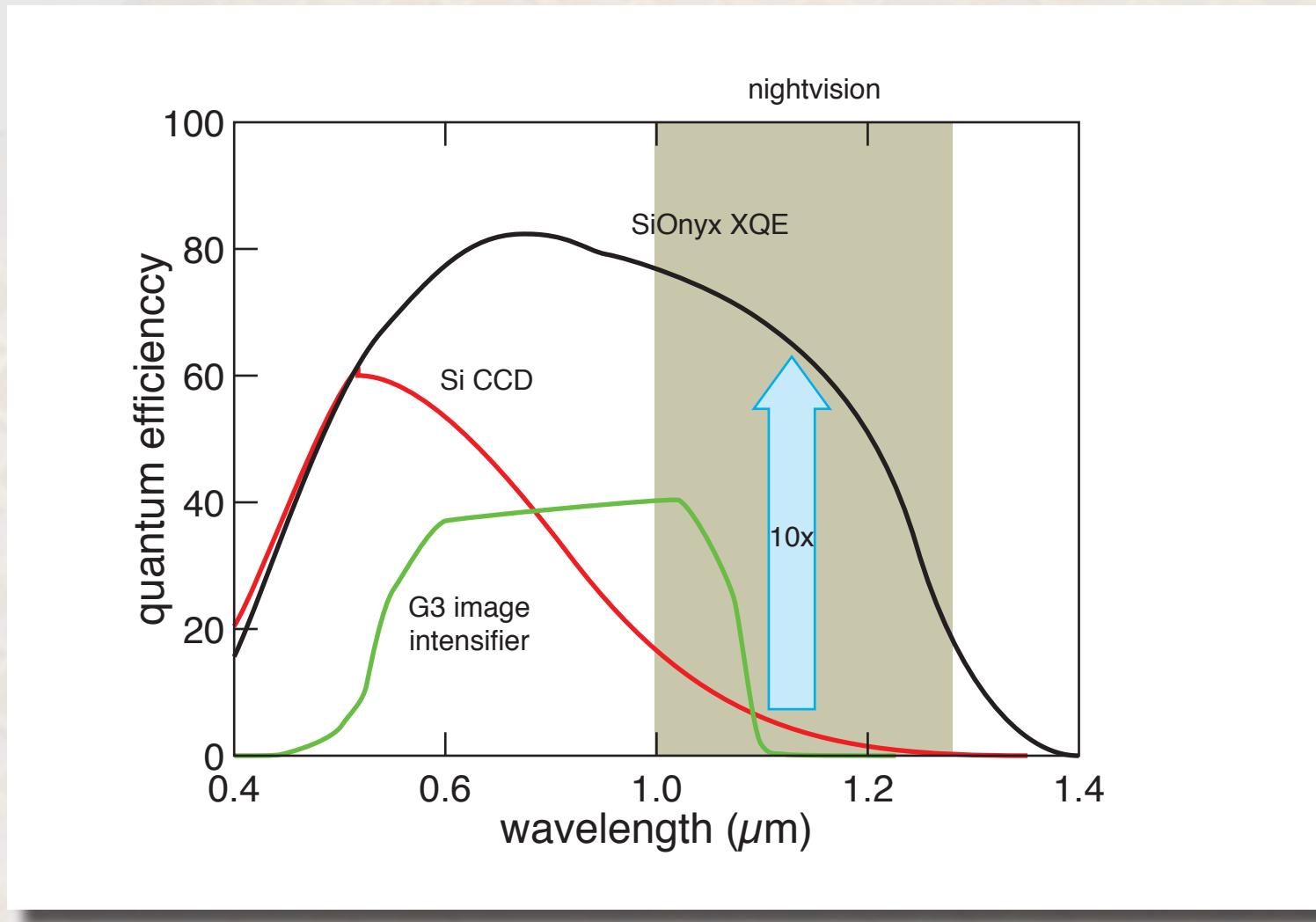
3 devices



1 properties

2 intermediate band

3 devices



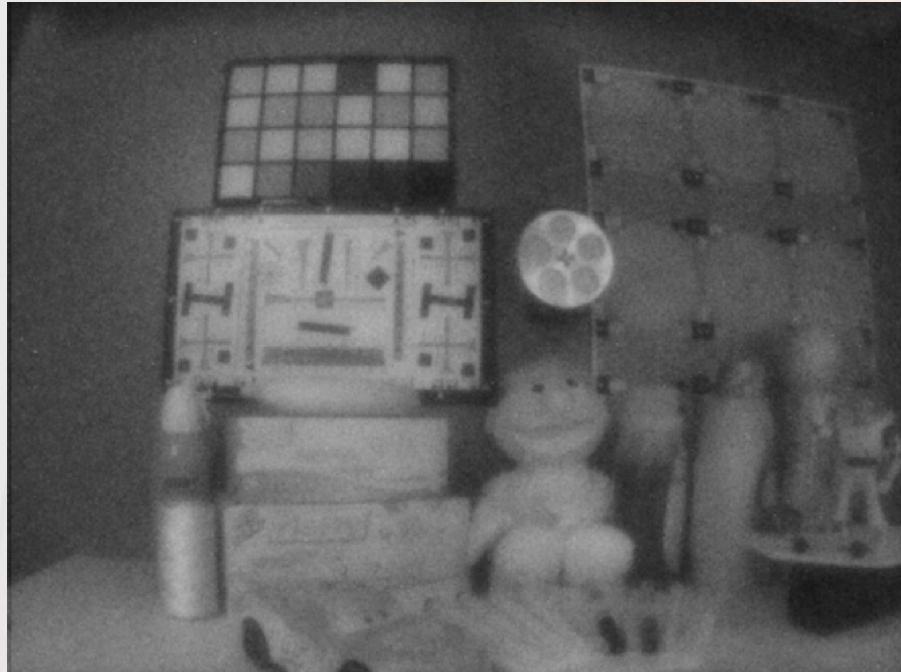
SiOnyx

1 properties

2 intermediate band

3 devices

dark room 1050 illumination



SiOnyx (F1.4, 33 ms, 24x)

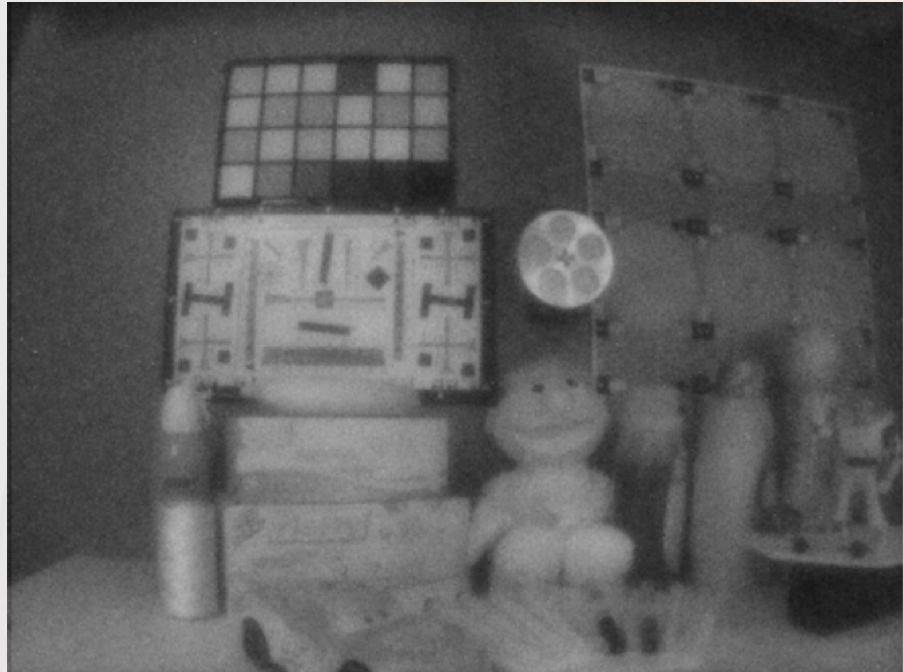


1 properties

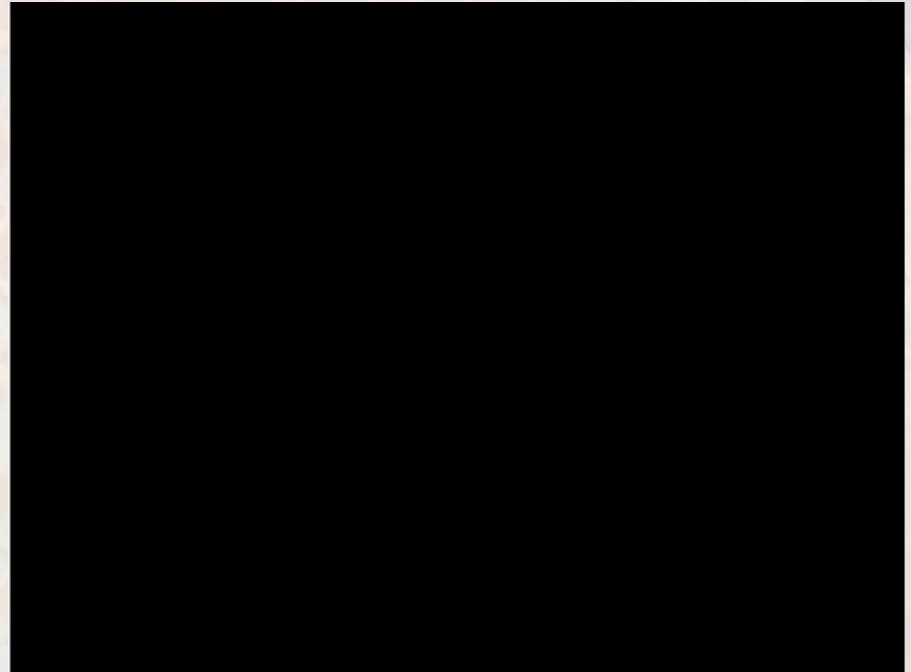
2 intermediate band

3 devices

dark room 1050 illumination



SiOnyx (F1.4, 33 ms, 24x)



reference (F1.4, 33 ms, 24x)

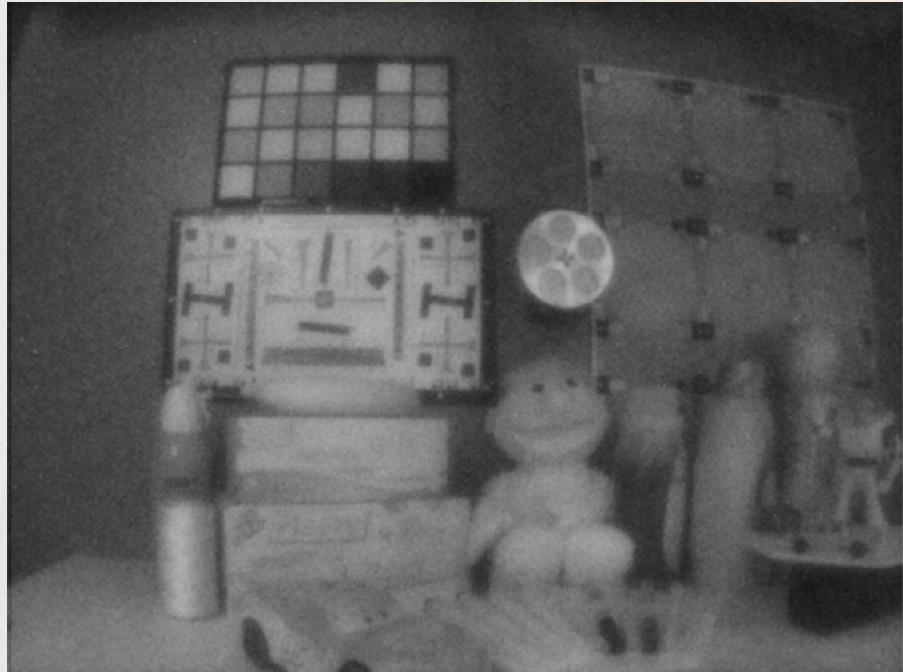


1 properties

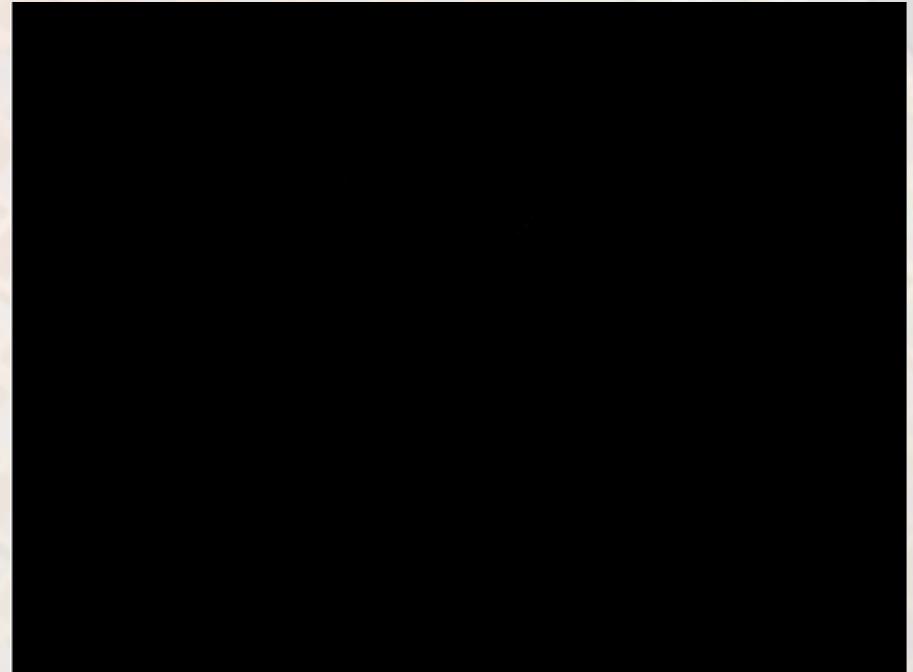
2 intermediate band

3 devices

dark room 1050 illumination



SiOnyx (F1.4, 33 ms, 24x)



reference (F1.4, 33 ms, 24x)

no image processing

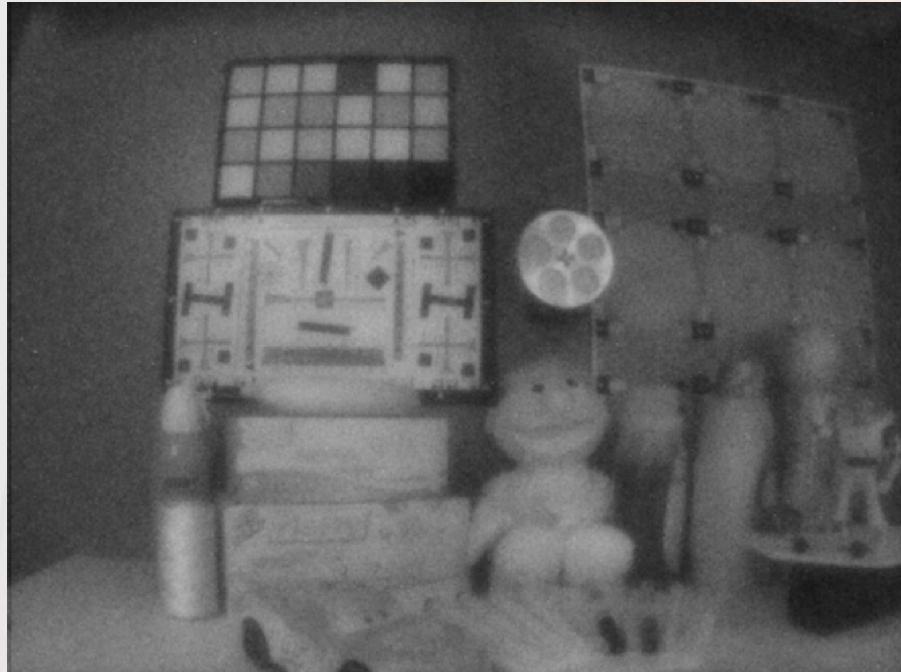


1 properties

2 intermediate band

3 devices

dark room 1050 illumination



SiOnyx (F1.4, 33 ms, 24x)



reference (F1.4, 33 ms, 24x)
2x DIGITAL GAIN ADDED

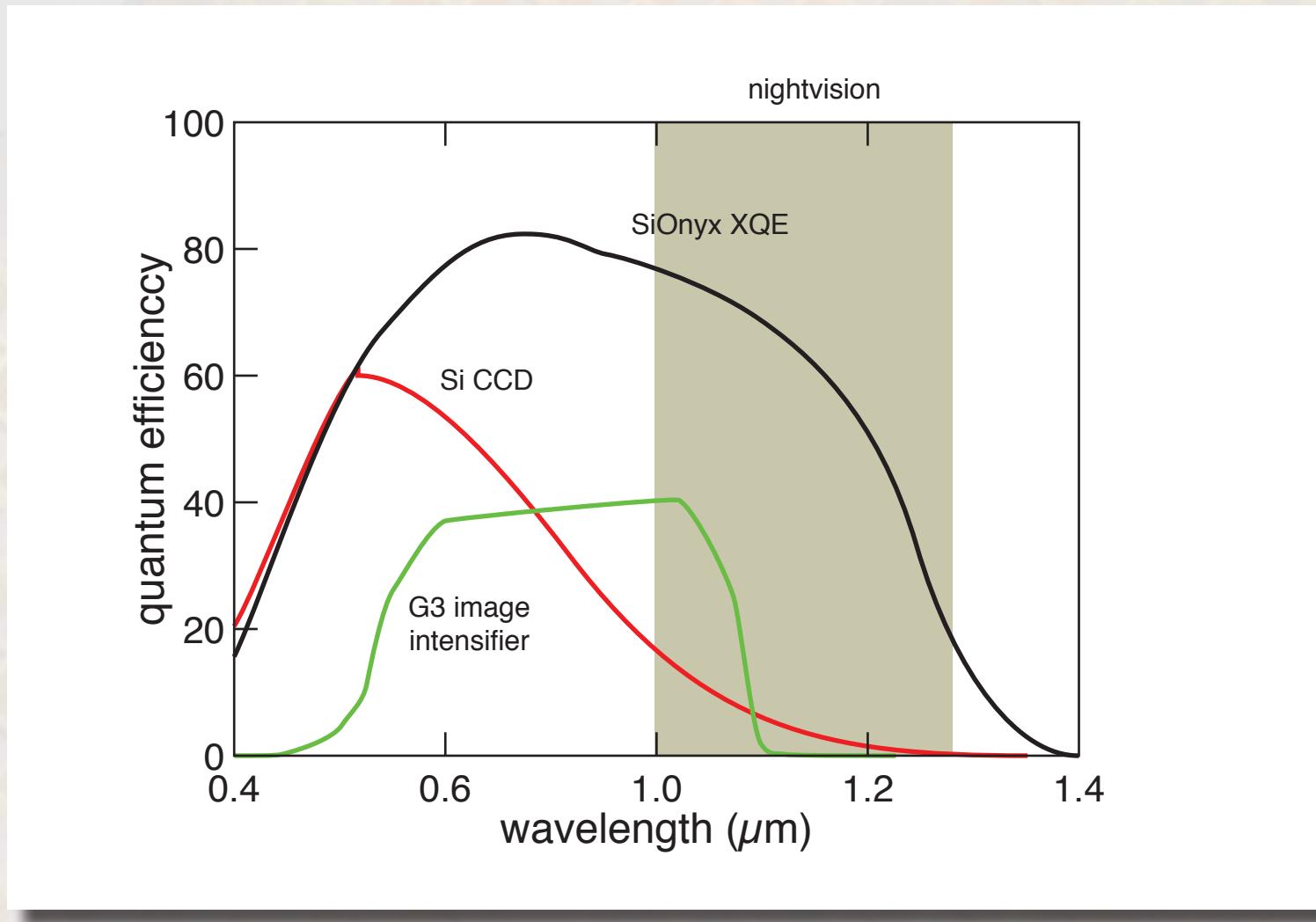
no image processing



1 properties

2 intermediate band

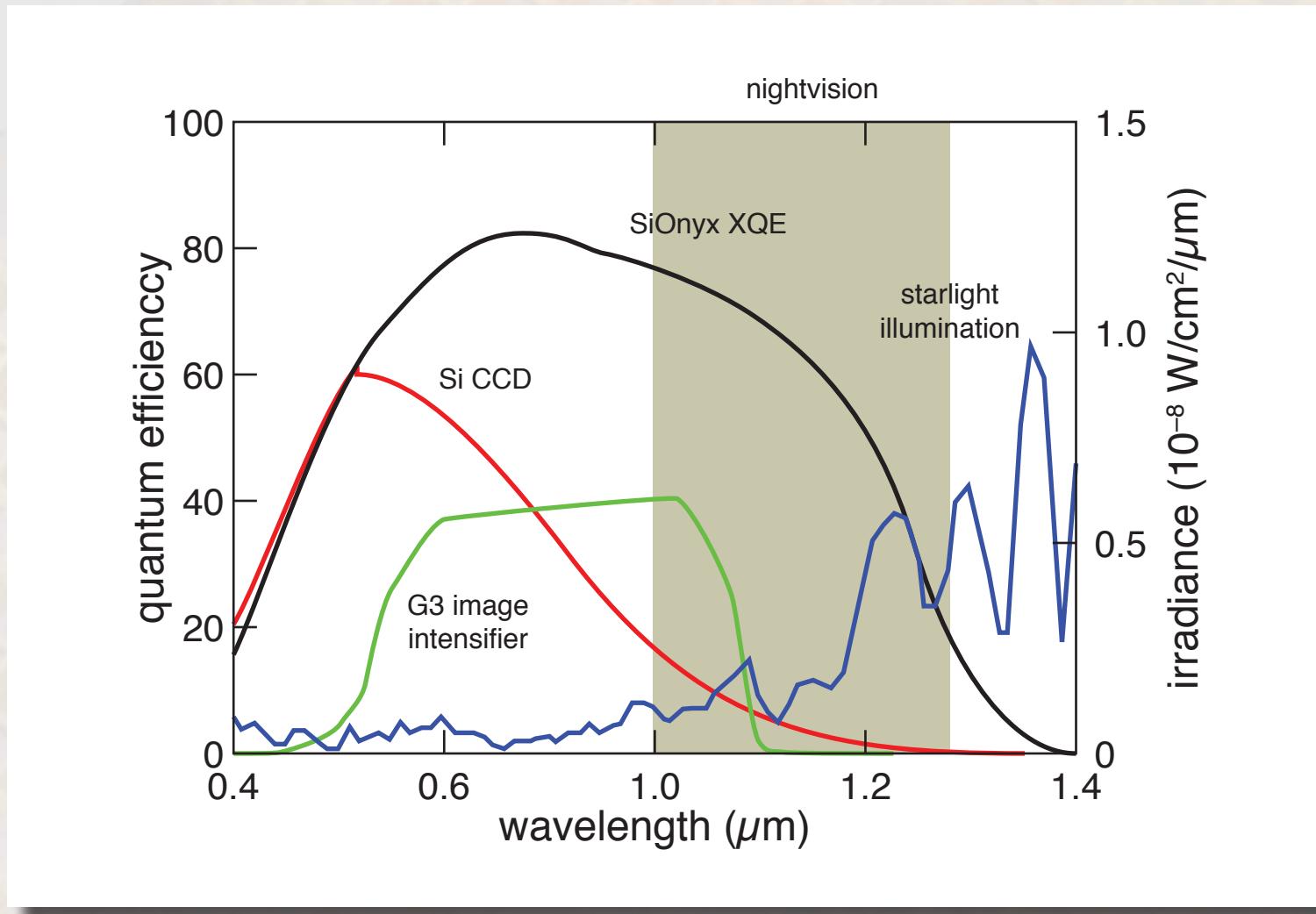
3 devices



1 properties

2 intermediate band

3 devices



1 properties

2 intermediate band

3 devices

starlight illumination

SiOnyx
25 mm
F1.4
30 fps



clear, moonless night (laser targeting spot: 30 μJ at 100 m)

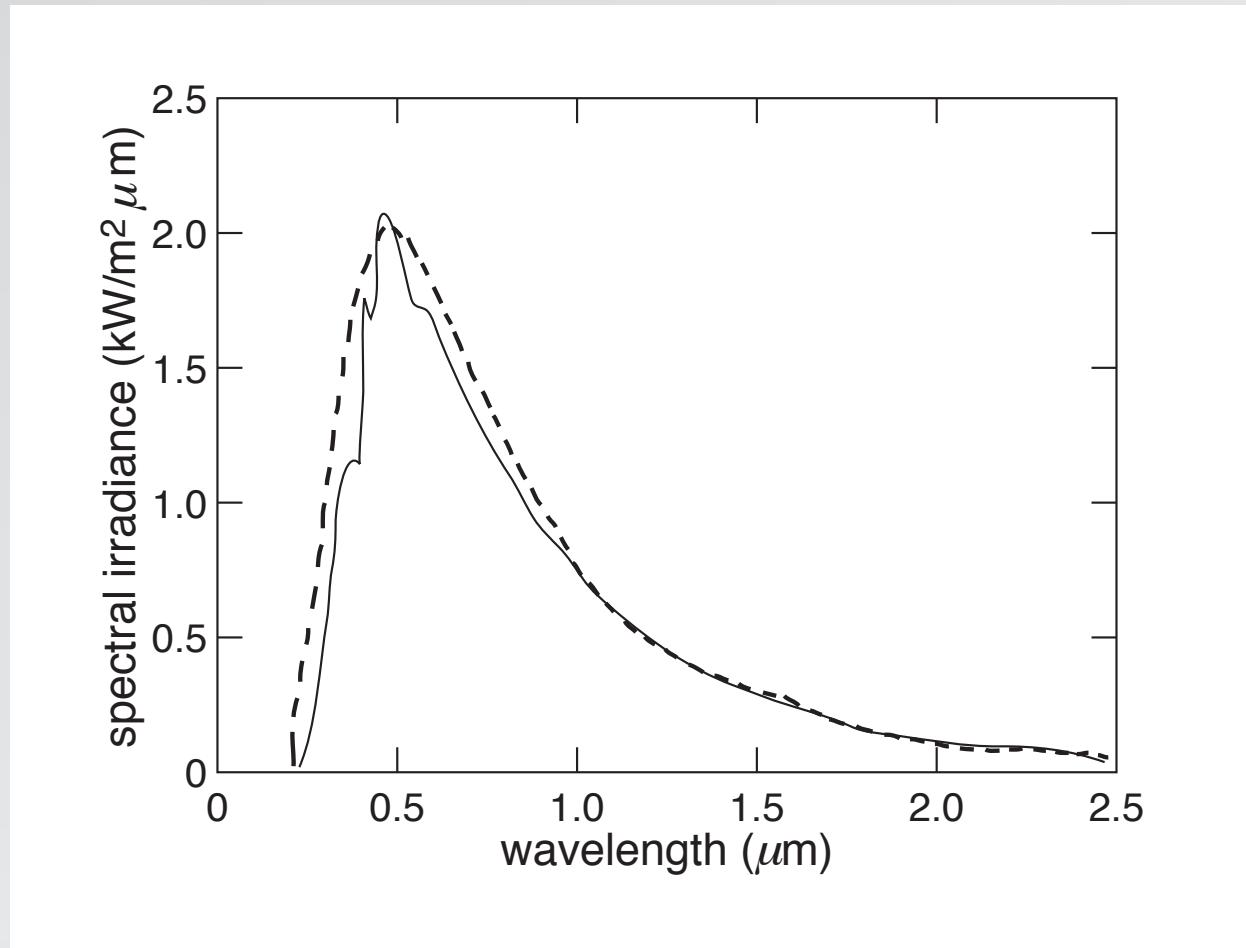


1 properties

2 intermediate band

3 devices

solar spectrum

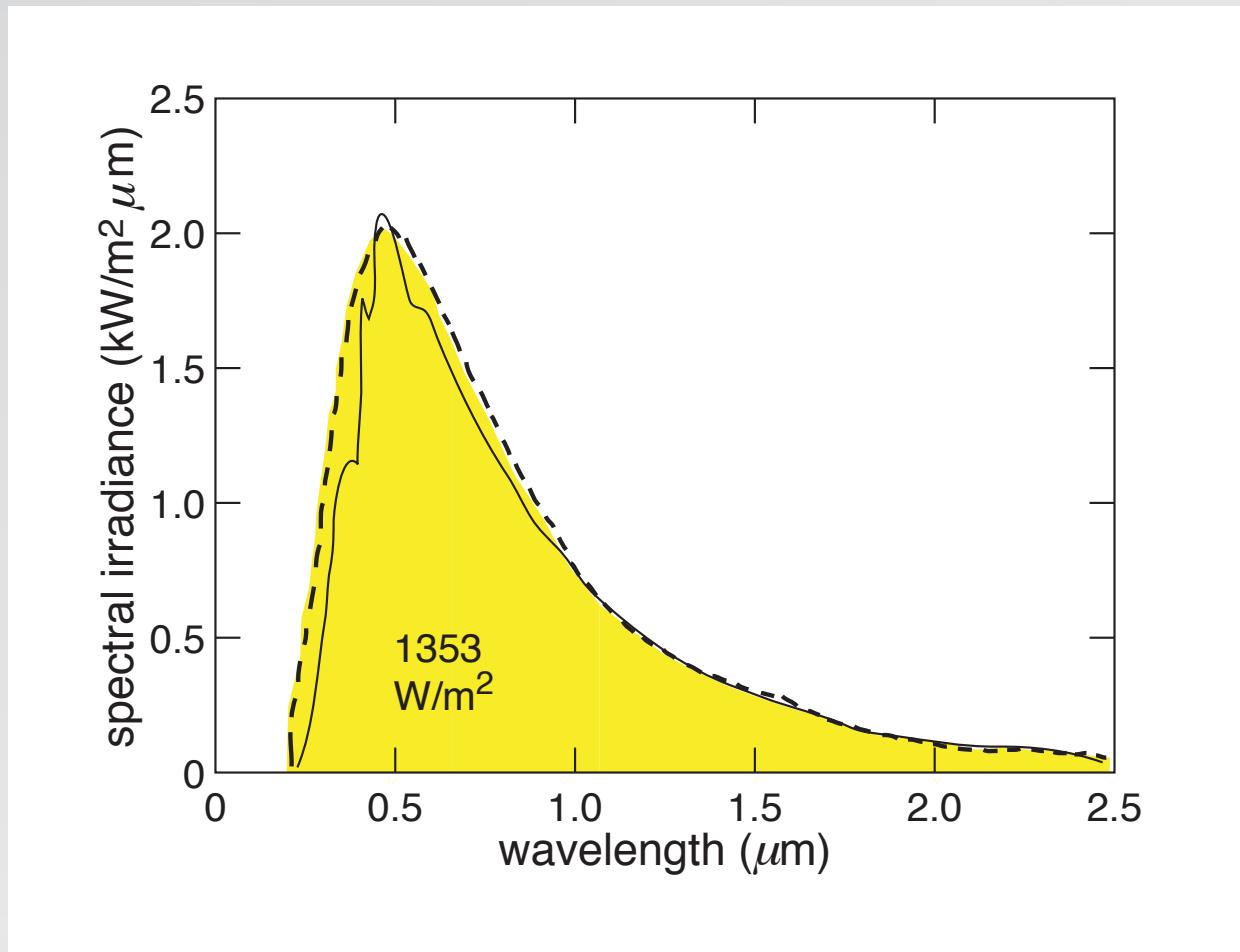


1 properties

2 intermediate band

3 devices

solar spectrum

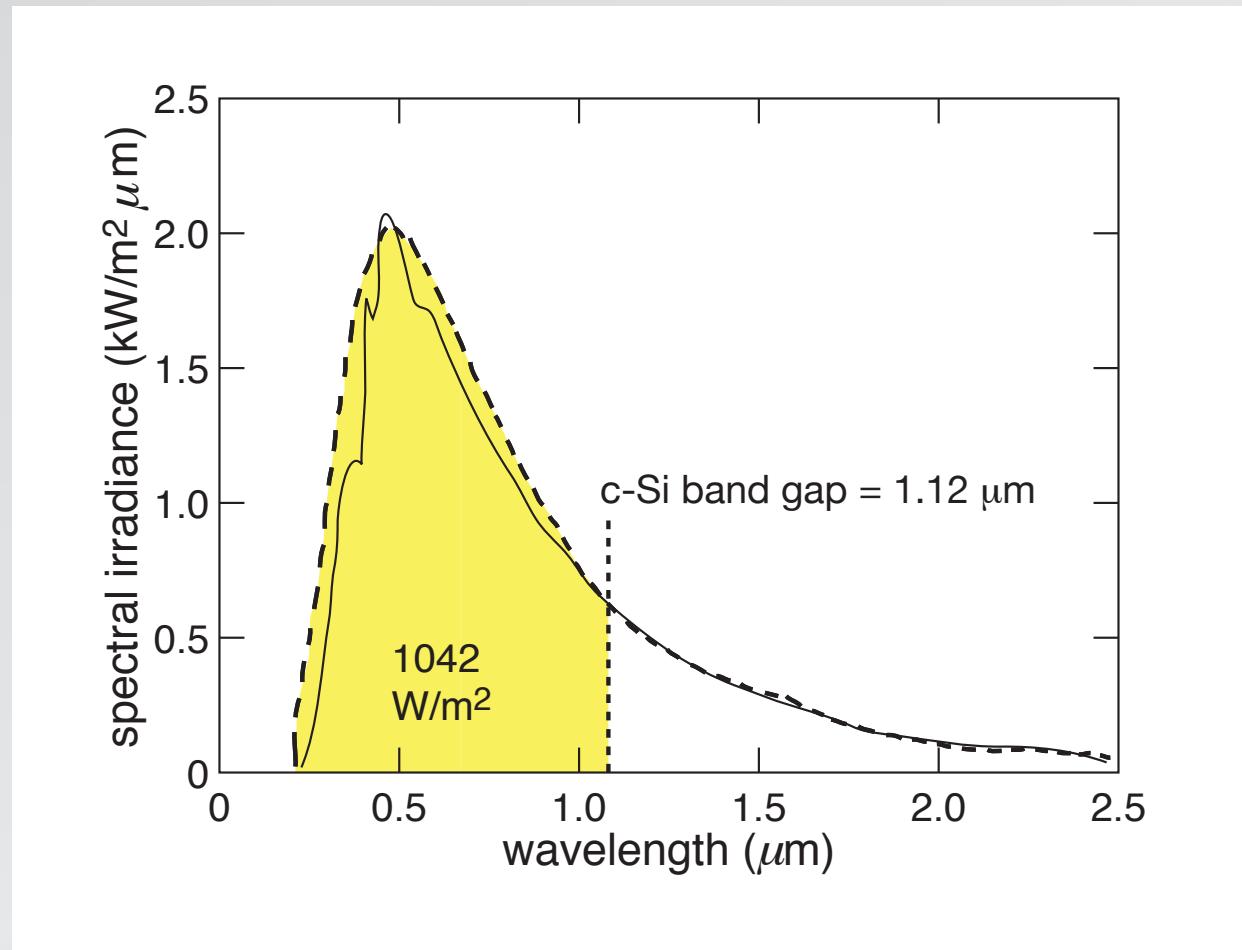


1 properties

2 intermediate band

3 devices

crystalline silicon: transparent to 23% of solar radiation

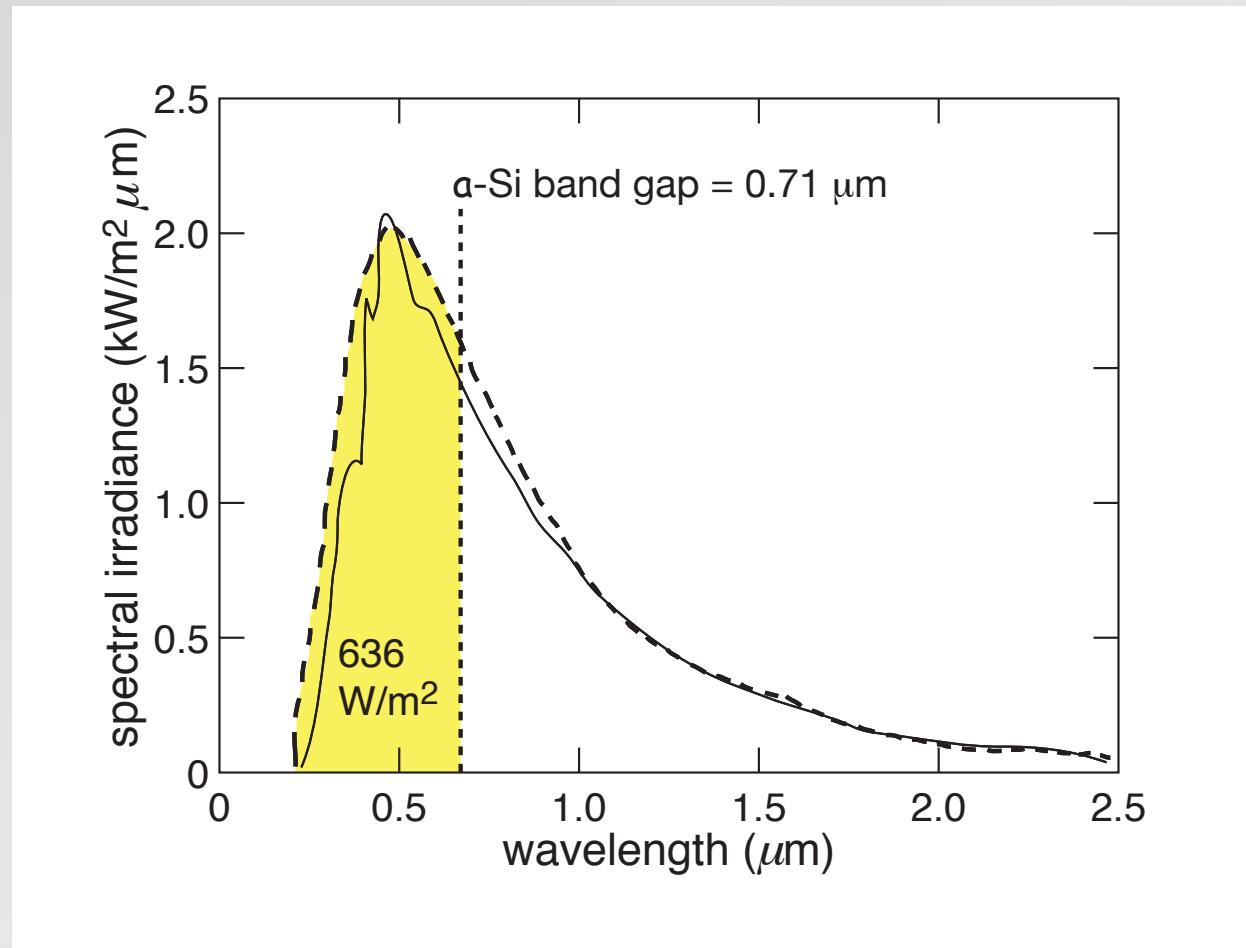


1 properties

2 intermediate band

3 devices

amorphous silicon: transparent to 53% of solar radiation

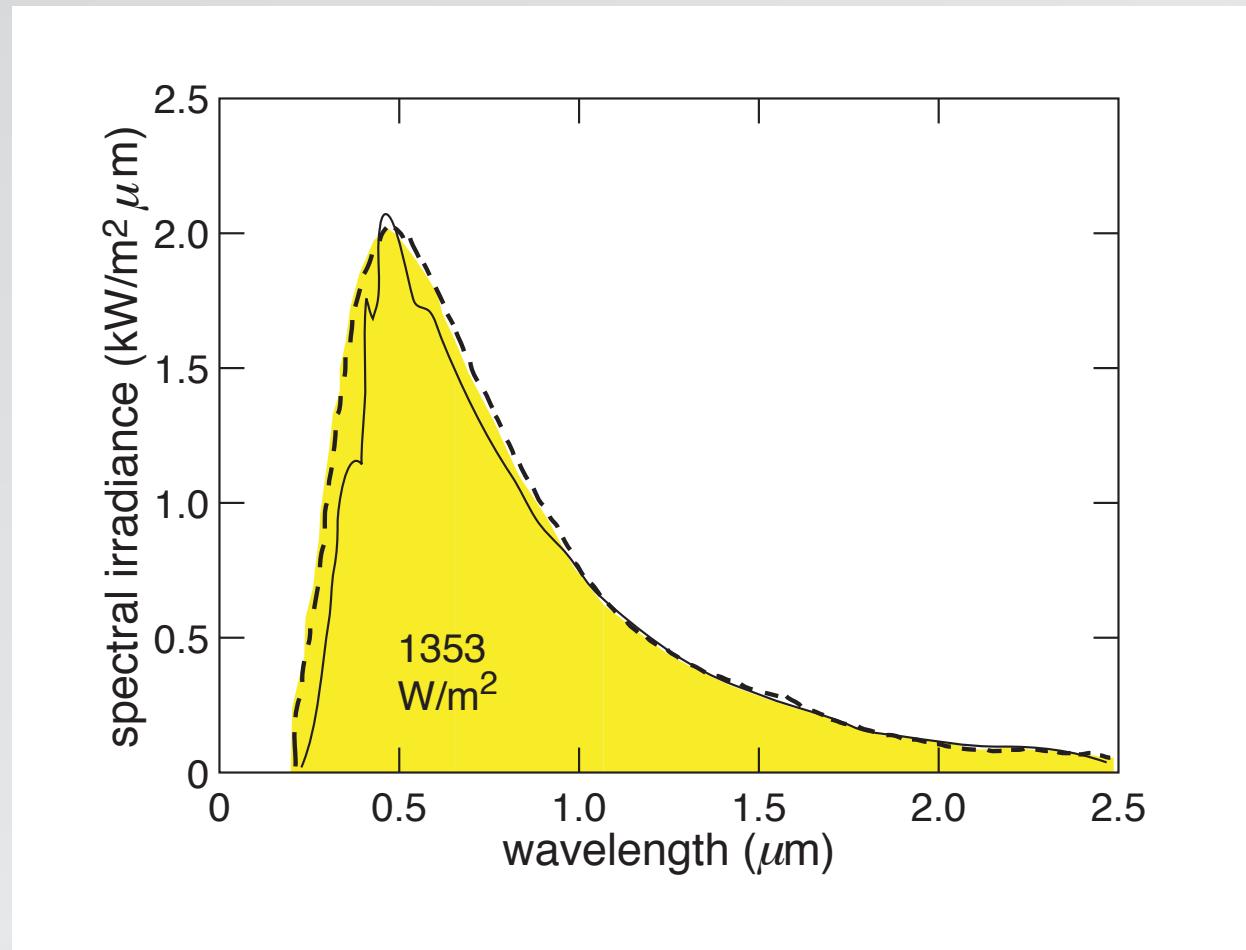


1 properties

2 intermediate band

3 devices

black silicon: potential to recover transmitted energy



1 properties

2 intermediate band

3 devices

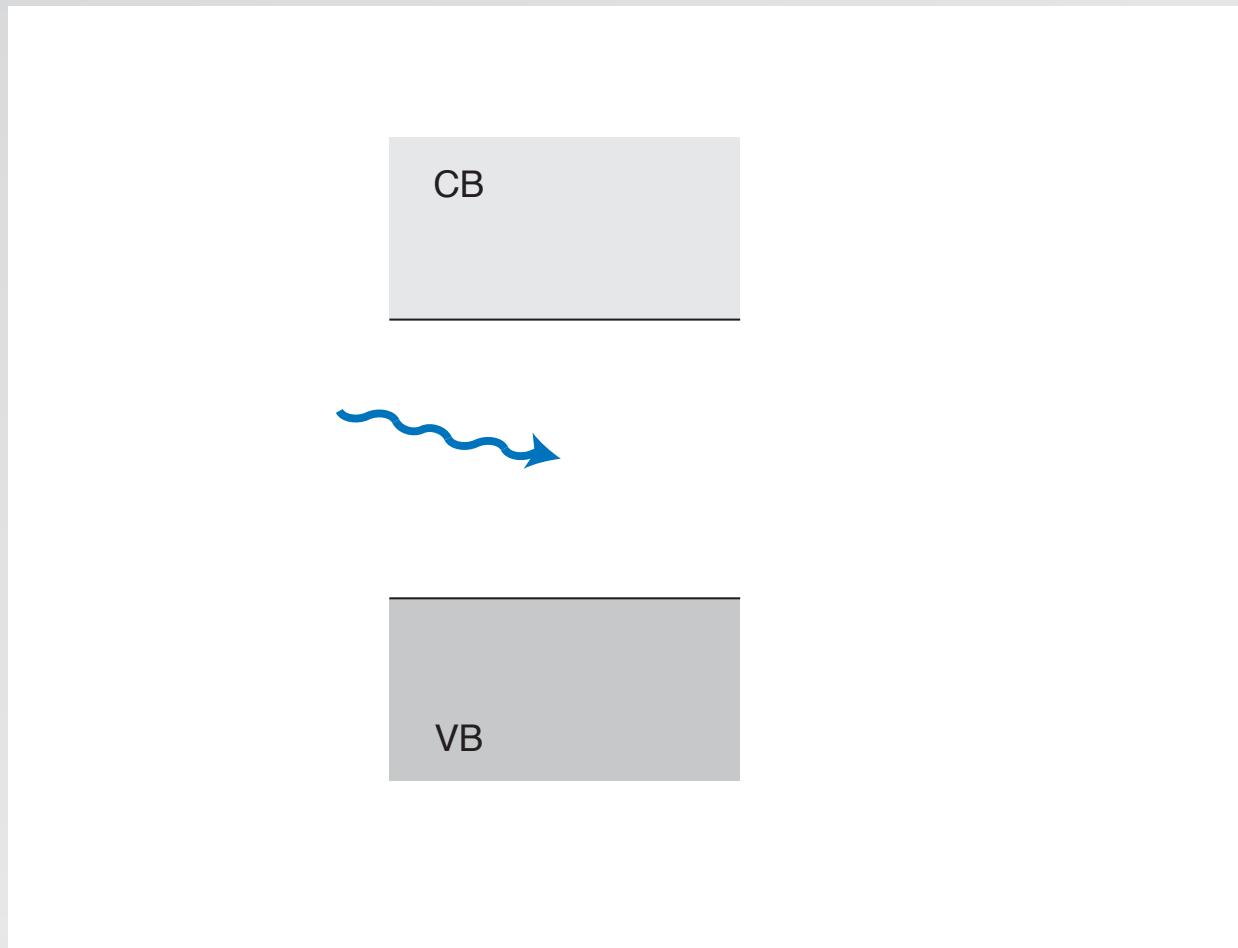


1 properties

2 intermediate band

3 devices

photon with gap energy

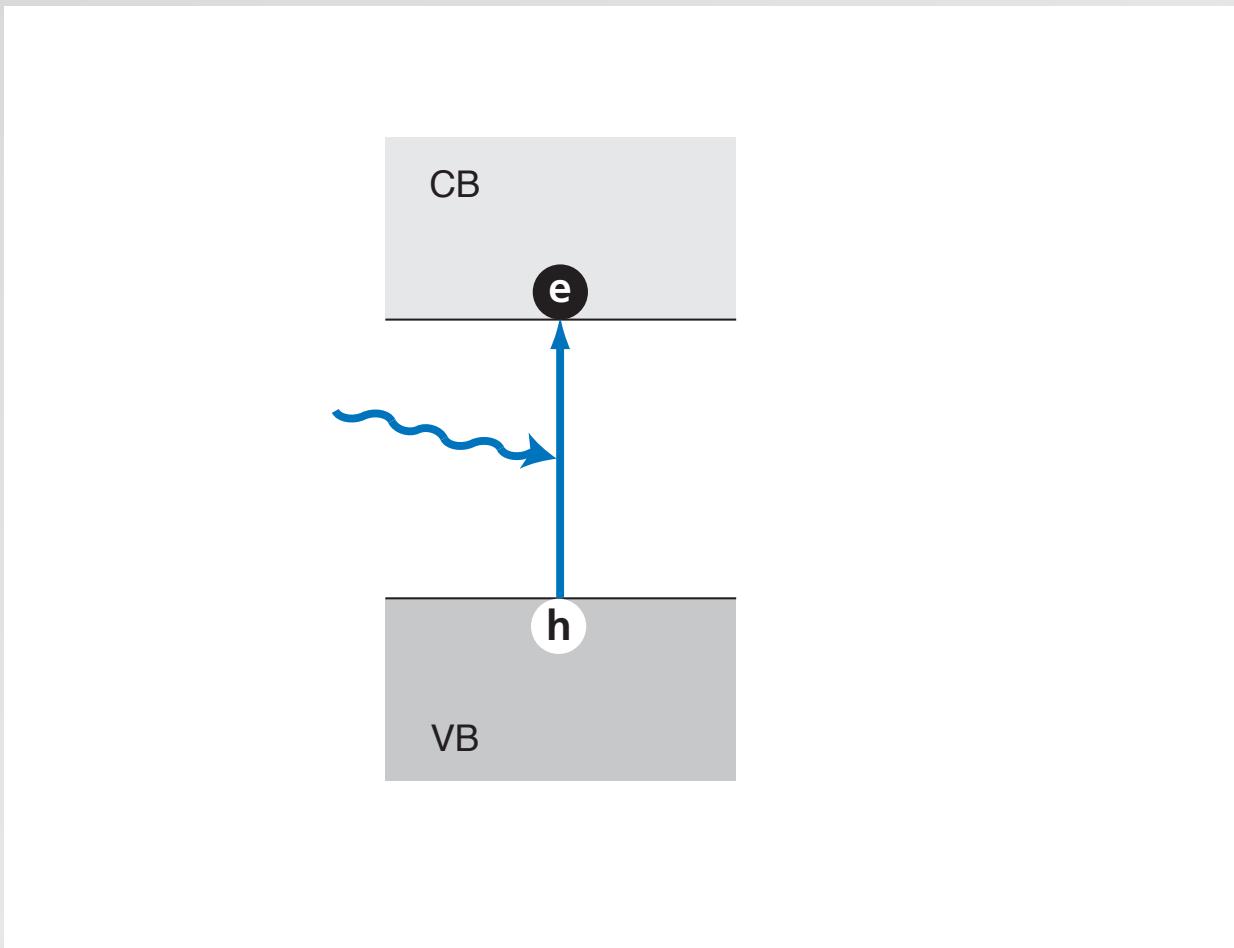


1 properties

2 intermediate band

3 devices

photon creates electron-hole pair...

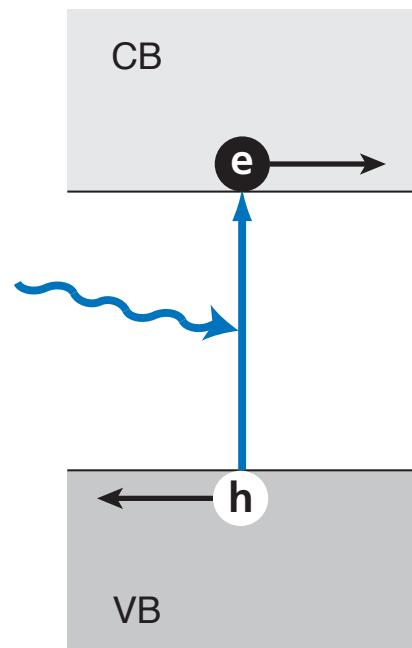


1 properties

2 intermediate band

3 devices

...whose energy can be extracted

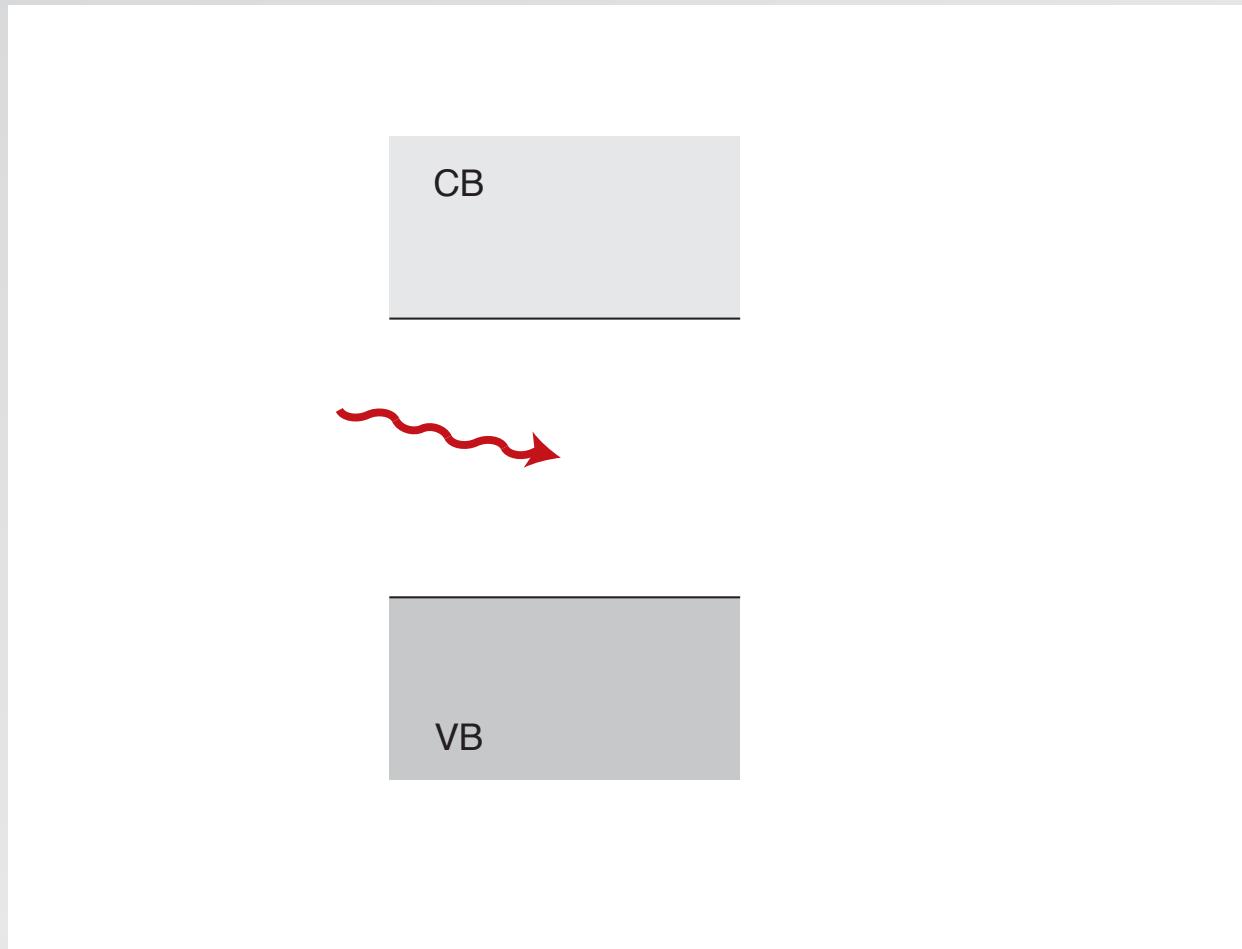


1 properties

2 intermediate band

3 devices

photons with energy smaller than gap...

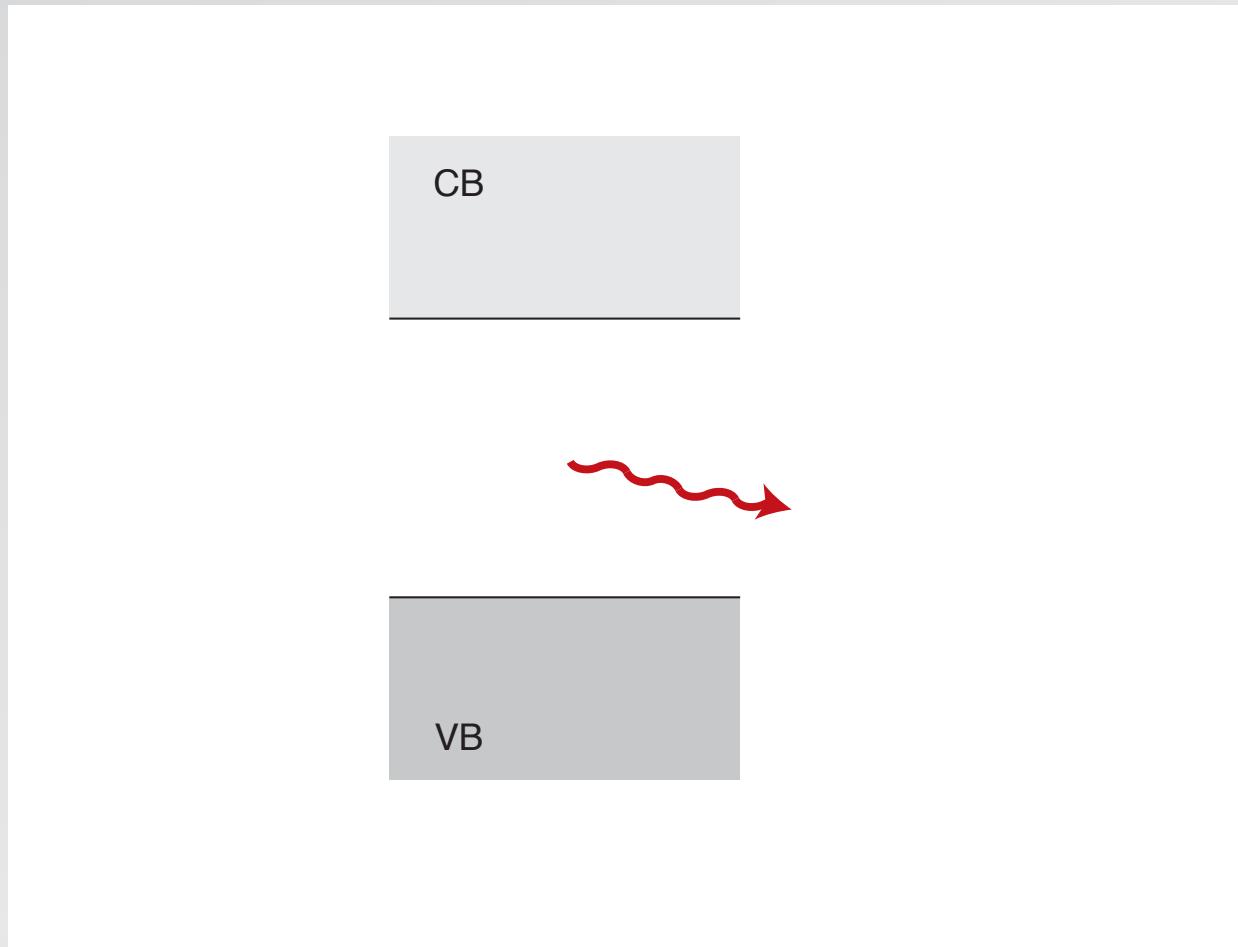


1 properties

2 intermediate band

3 devices

...do not get absorbed

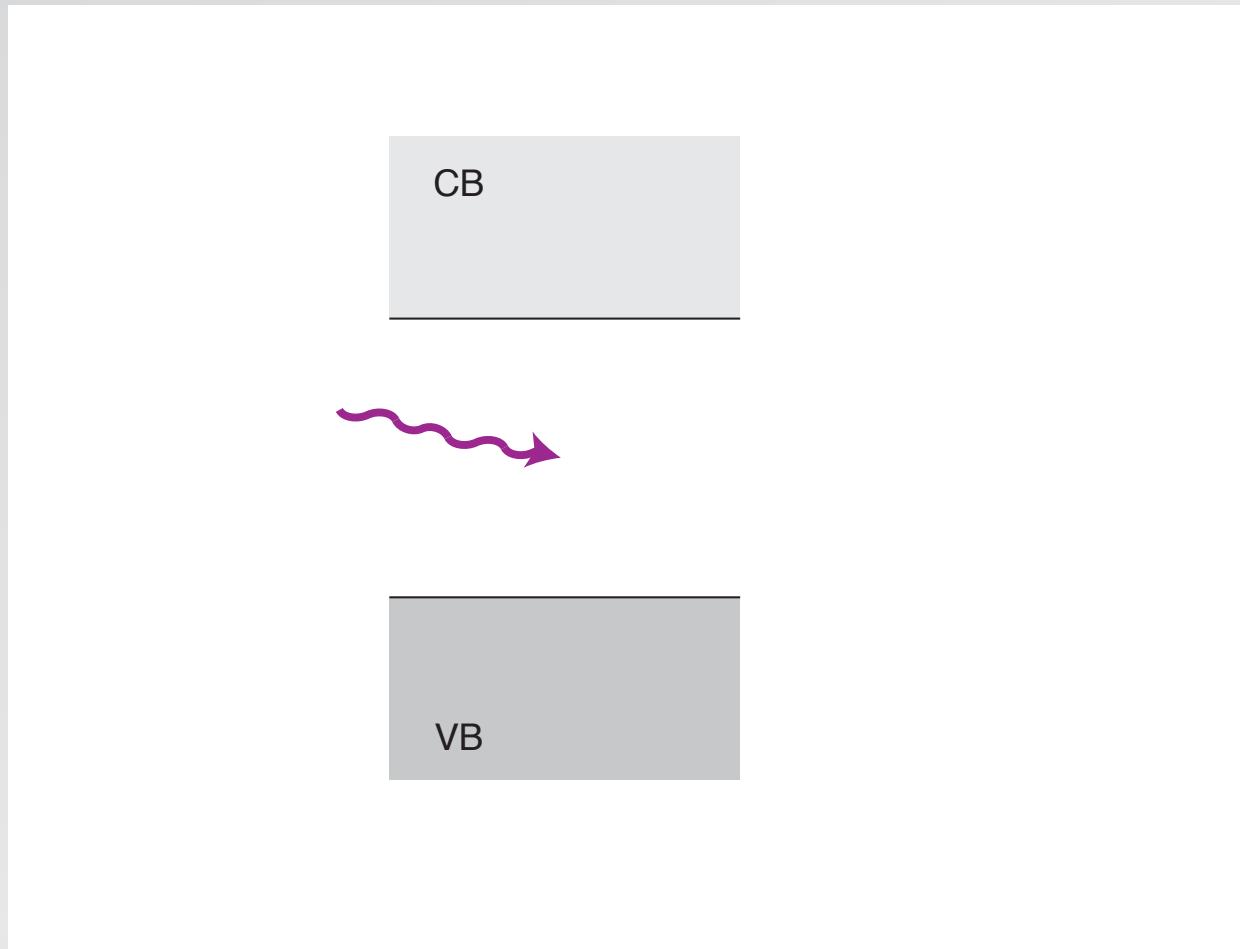


1 properties

2 intermediate band

3 devices

photons with energy larger than the gap...

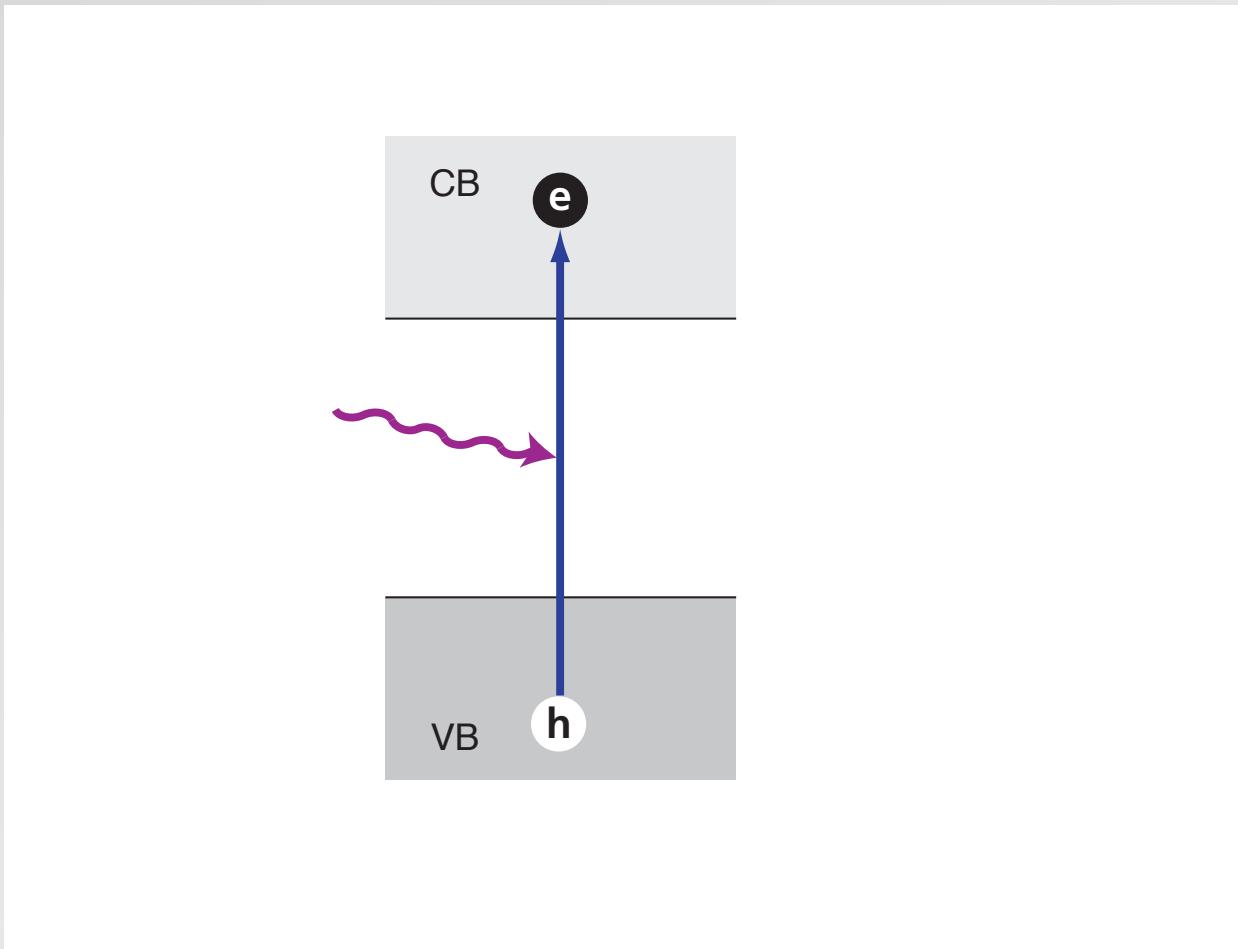


1 properties

2 intermediate band

3 devices

...create electron-hole pairs with excess energy...

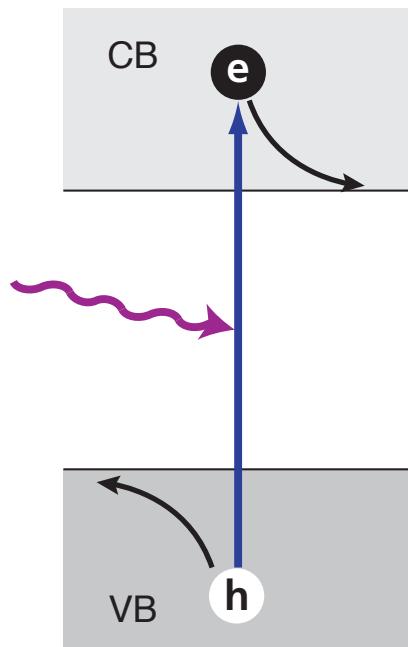


1 properties

2 intermediate band

3 devices

...which is lost rapidly

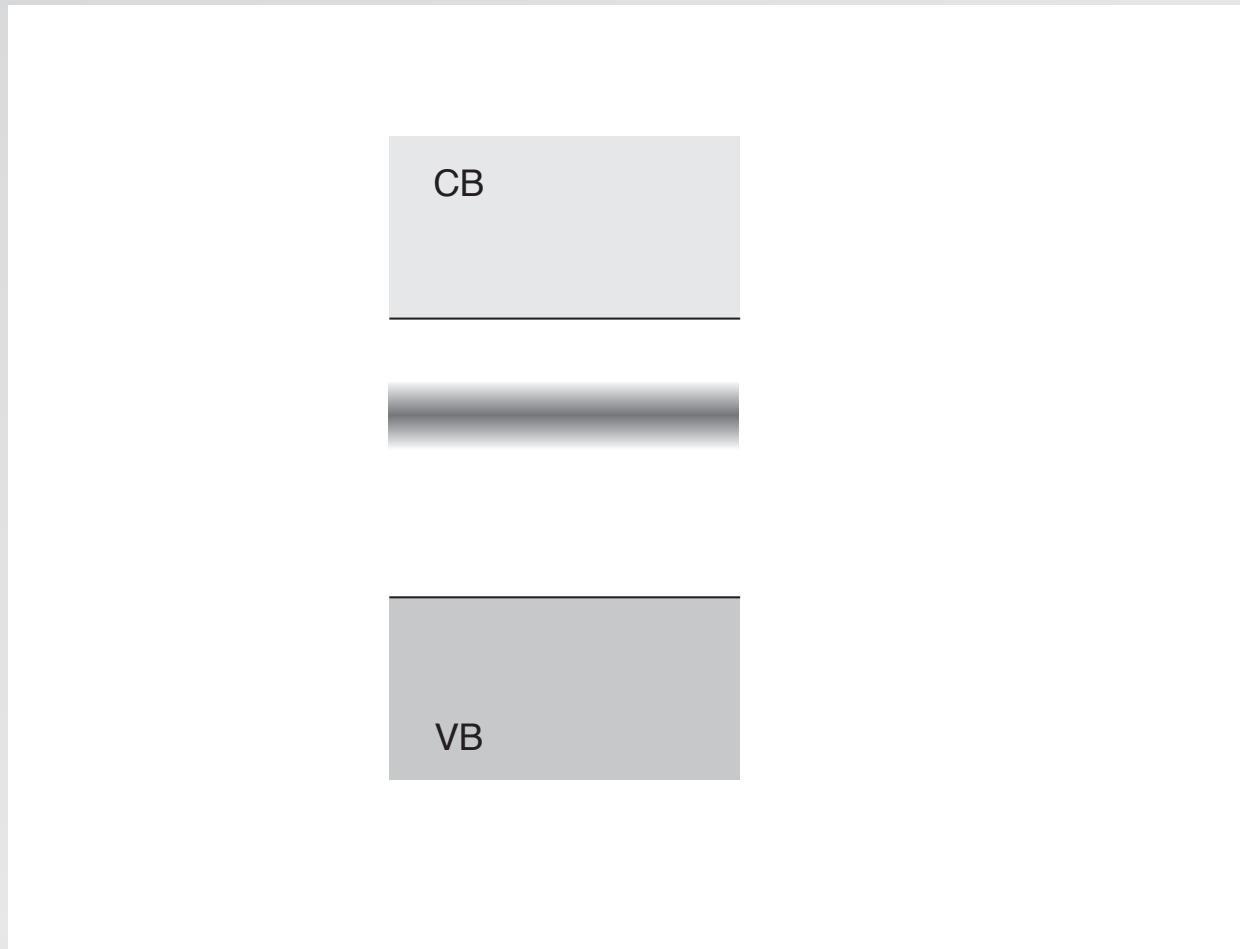


1 properties

2 intermediate band

3 devices

black silicon has an intermediate band

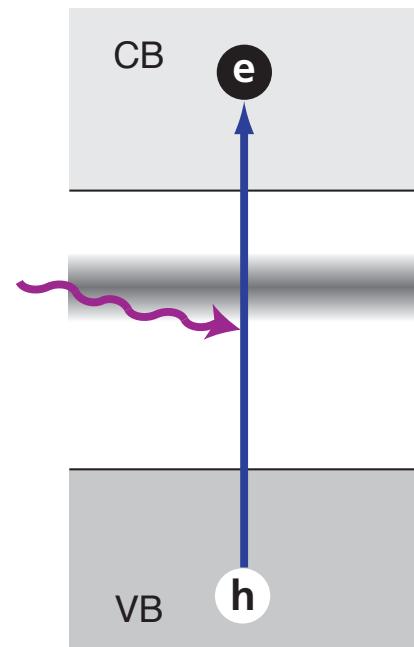


1 properties

2 intermediate band

3 devices

absorbs same photons as ordinary silicon...

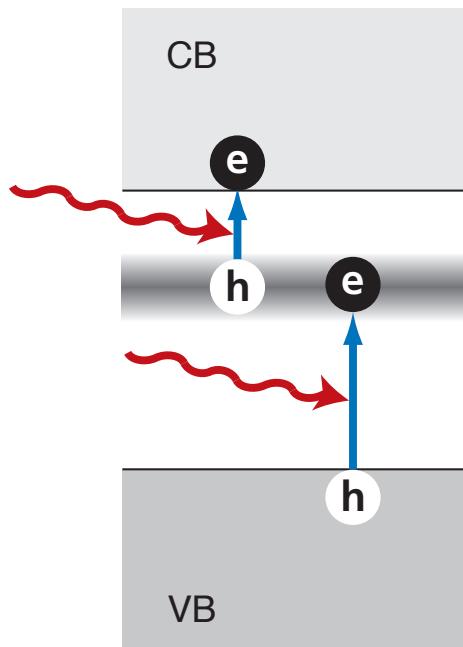


1 properties

2 intermediate band

3 devices

...but extends absorption to longer wavelengths

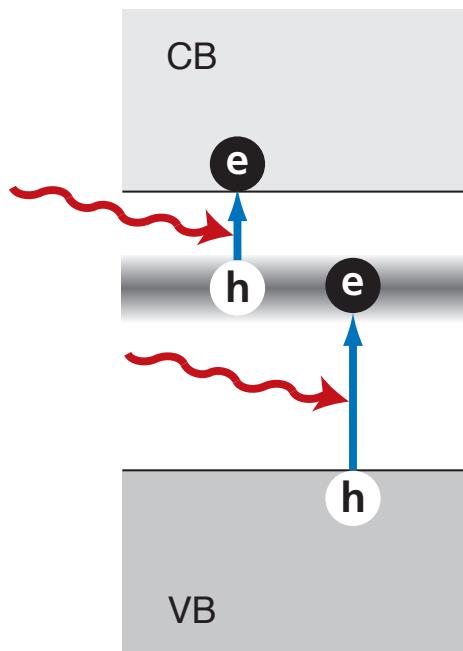


1 properties

2 intermediate band

3 devices

could theoretically get efficiencies over 50%

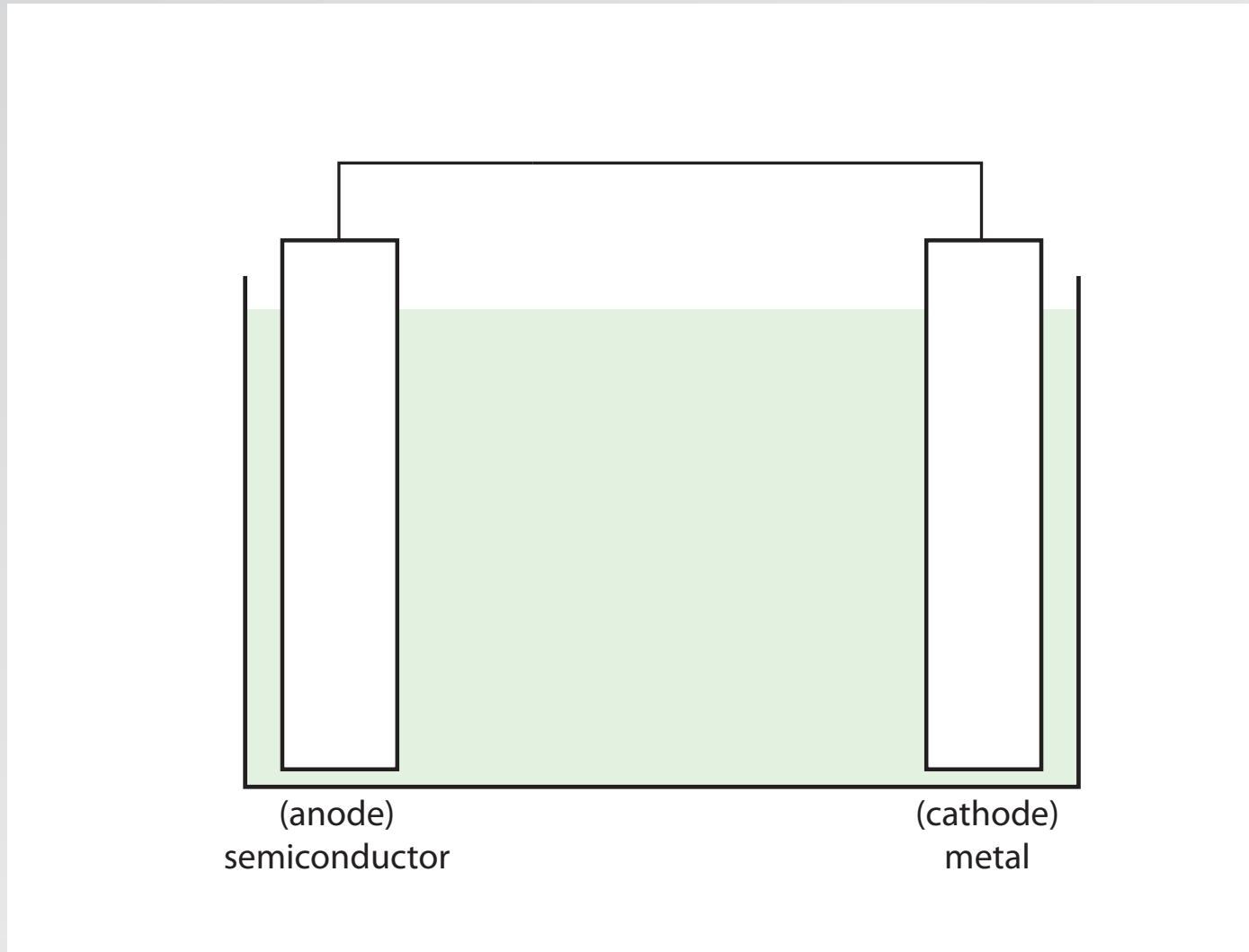


1 properties

2 intermediate band

3 devices

water splitting

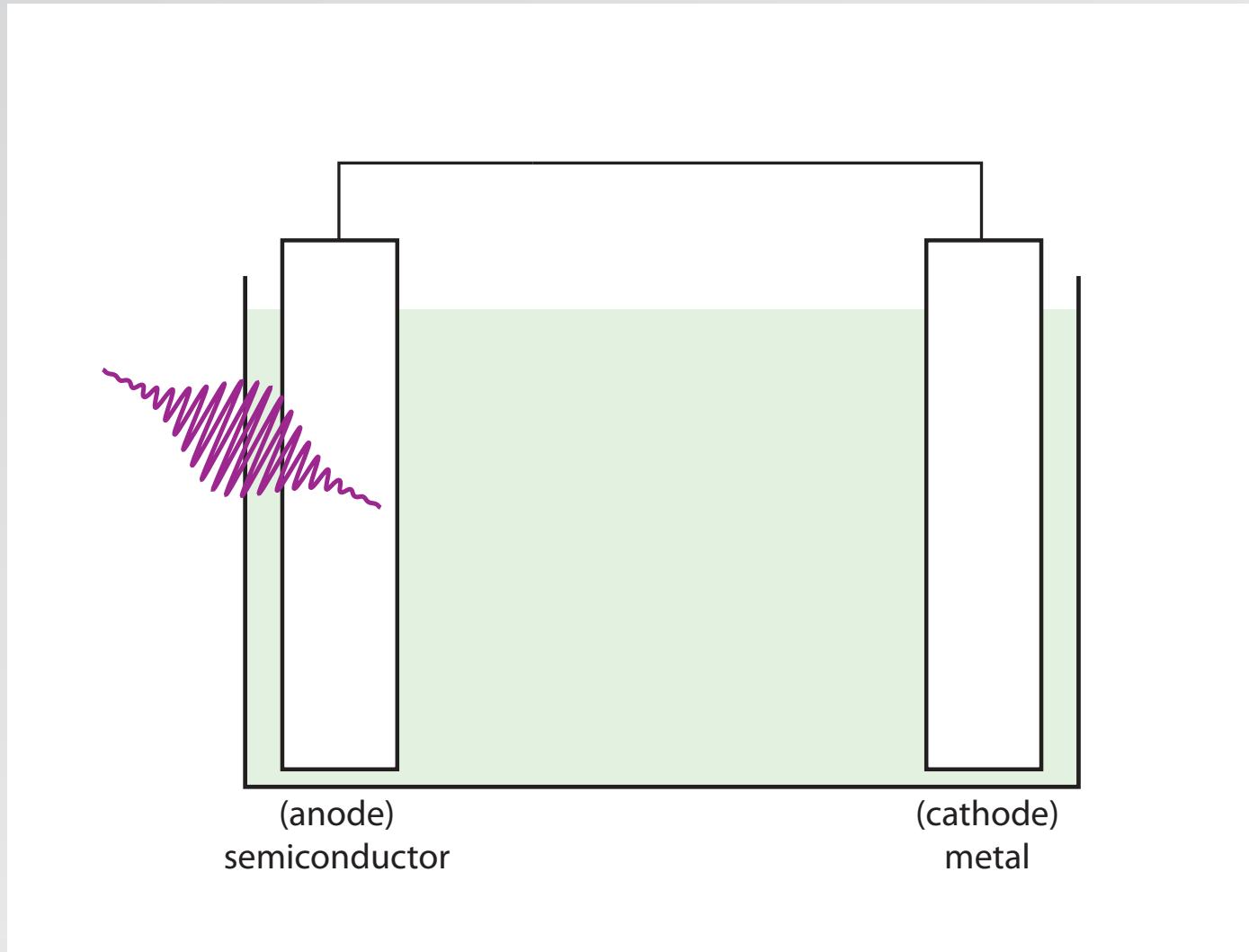


1 properties

2 intermediate band

3 devices

water splitting

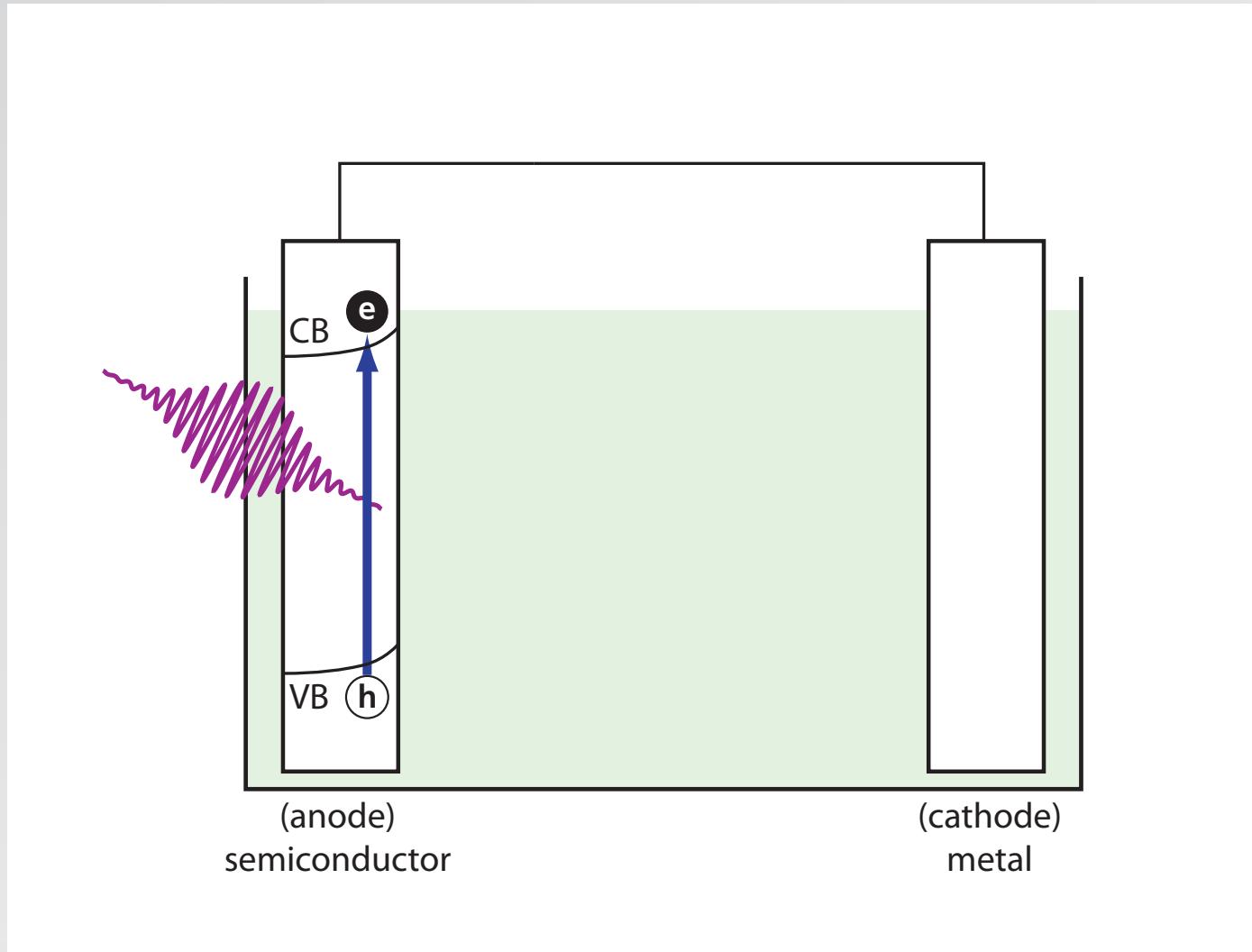


1 properties

2 intermediate band

3 devices

water splitting

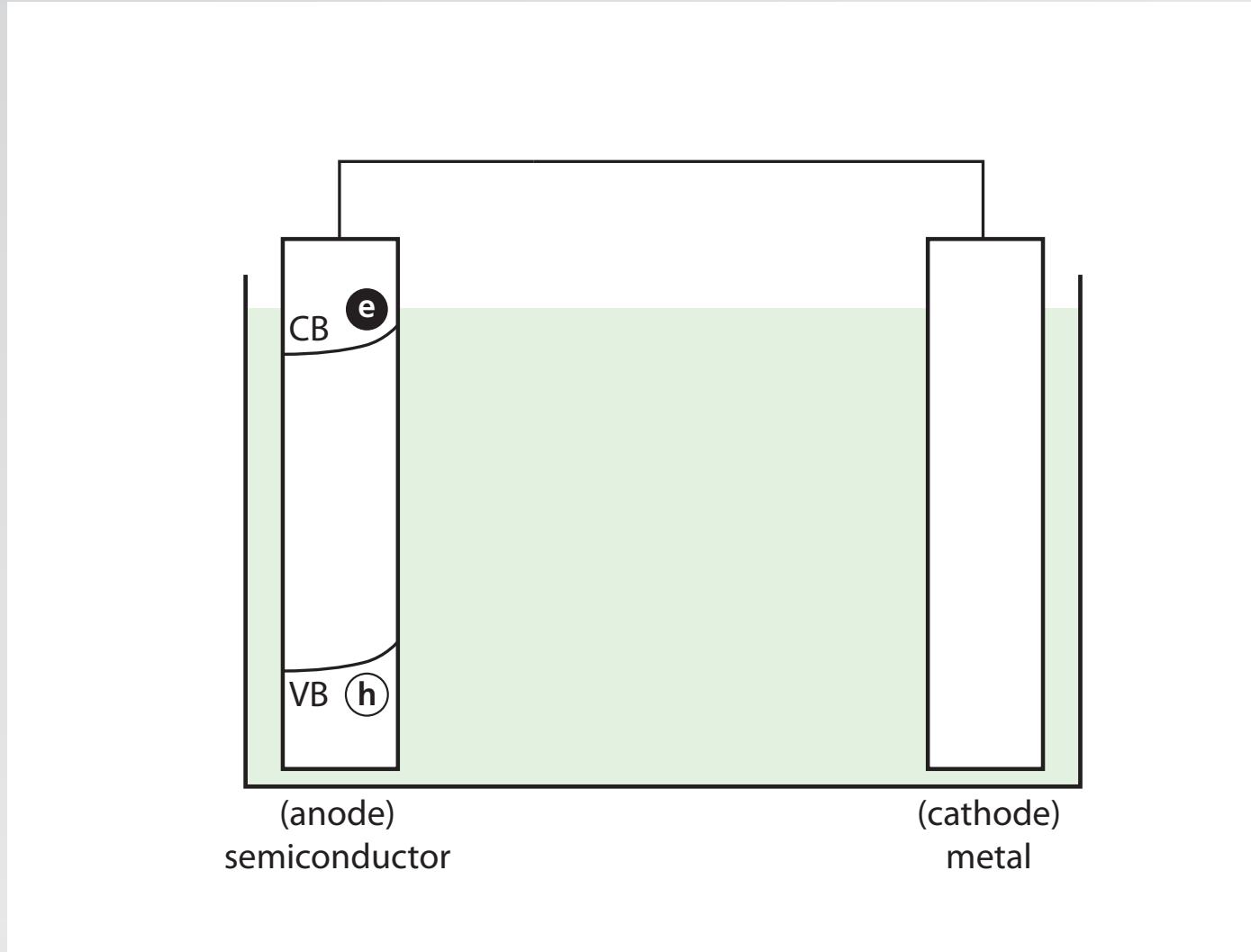


1 properties

2 intermediate band

3 devices

water splitting

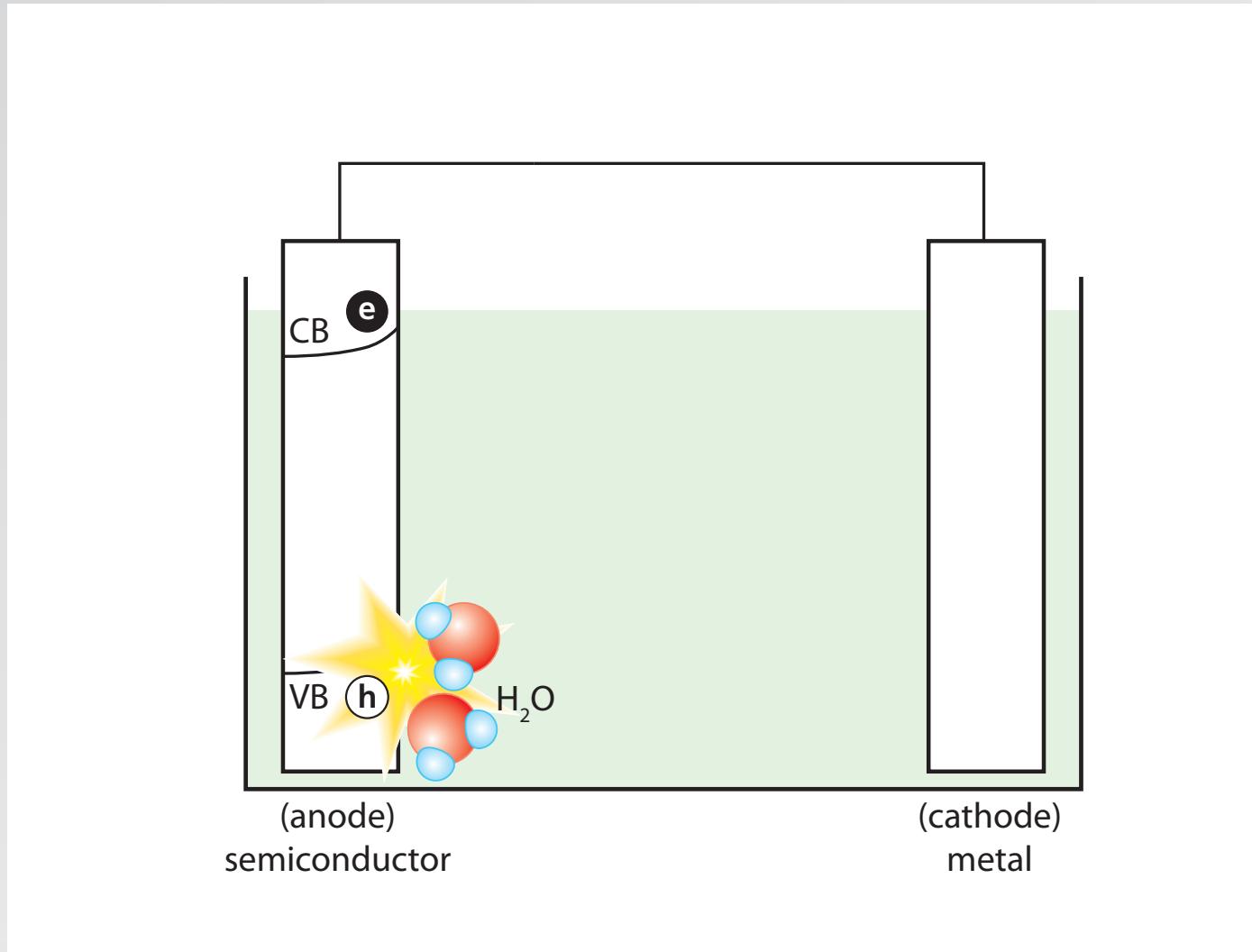


1 properties

2 intermediate band

3 devices

water splitting

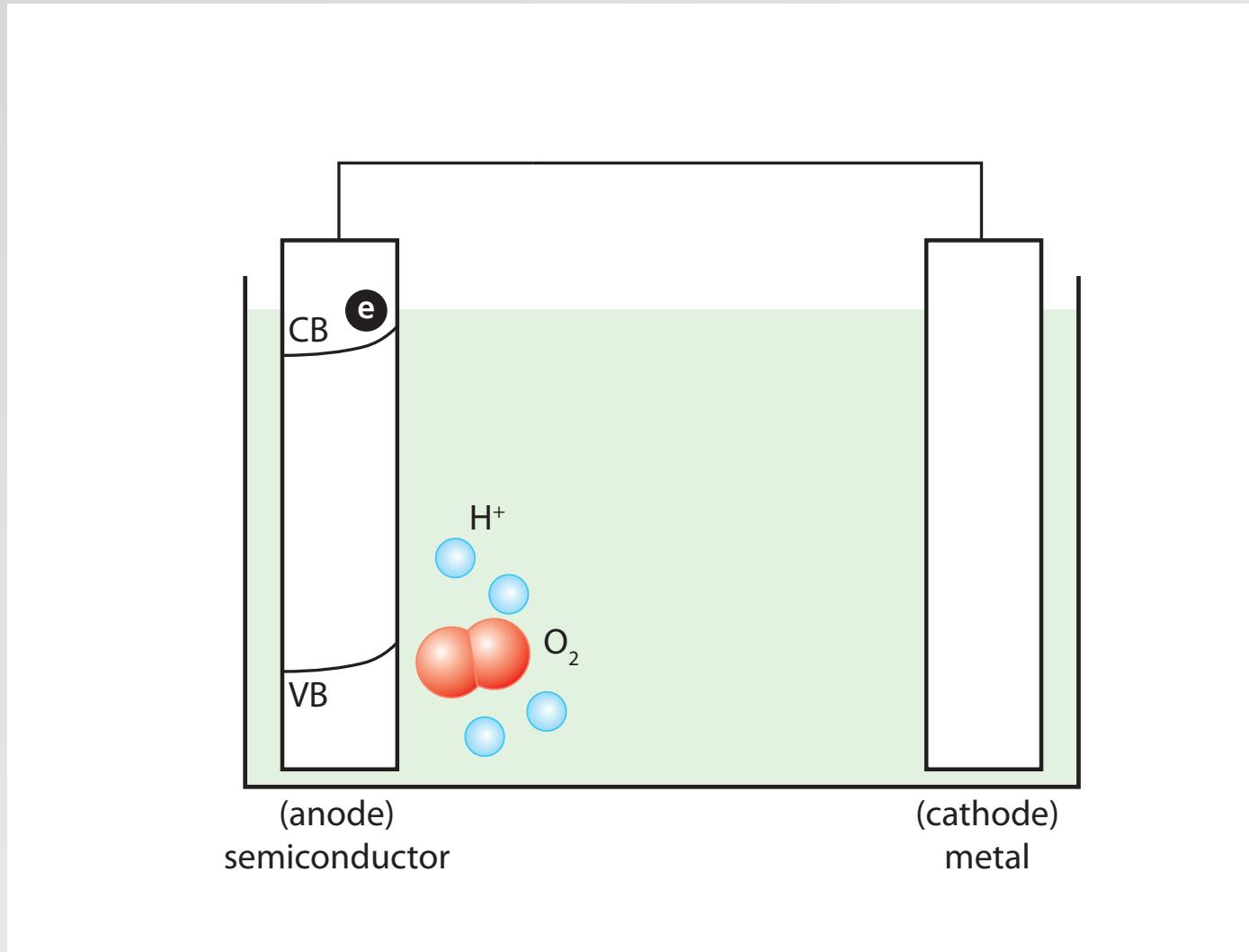


1 properties

2 intermediate band

3 devices

water splitting

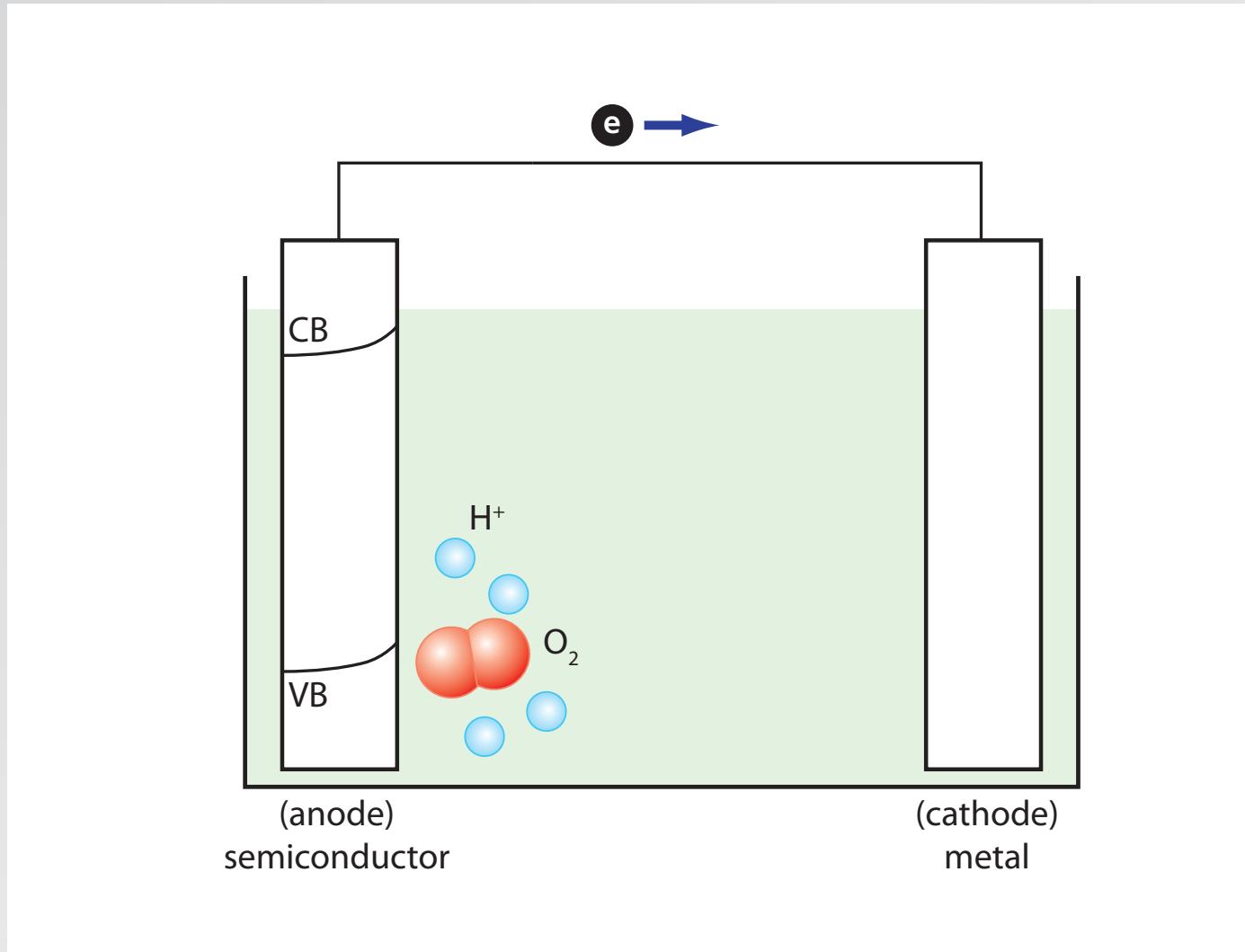


1 properties

2 intermediate band

3 devices

water splitting

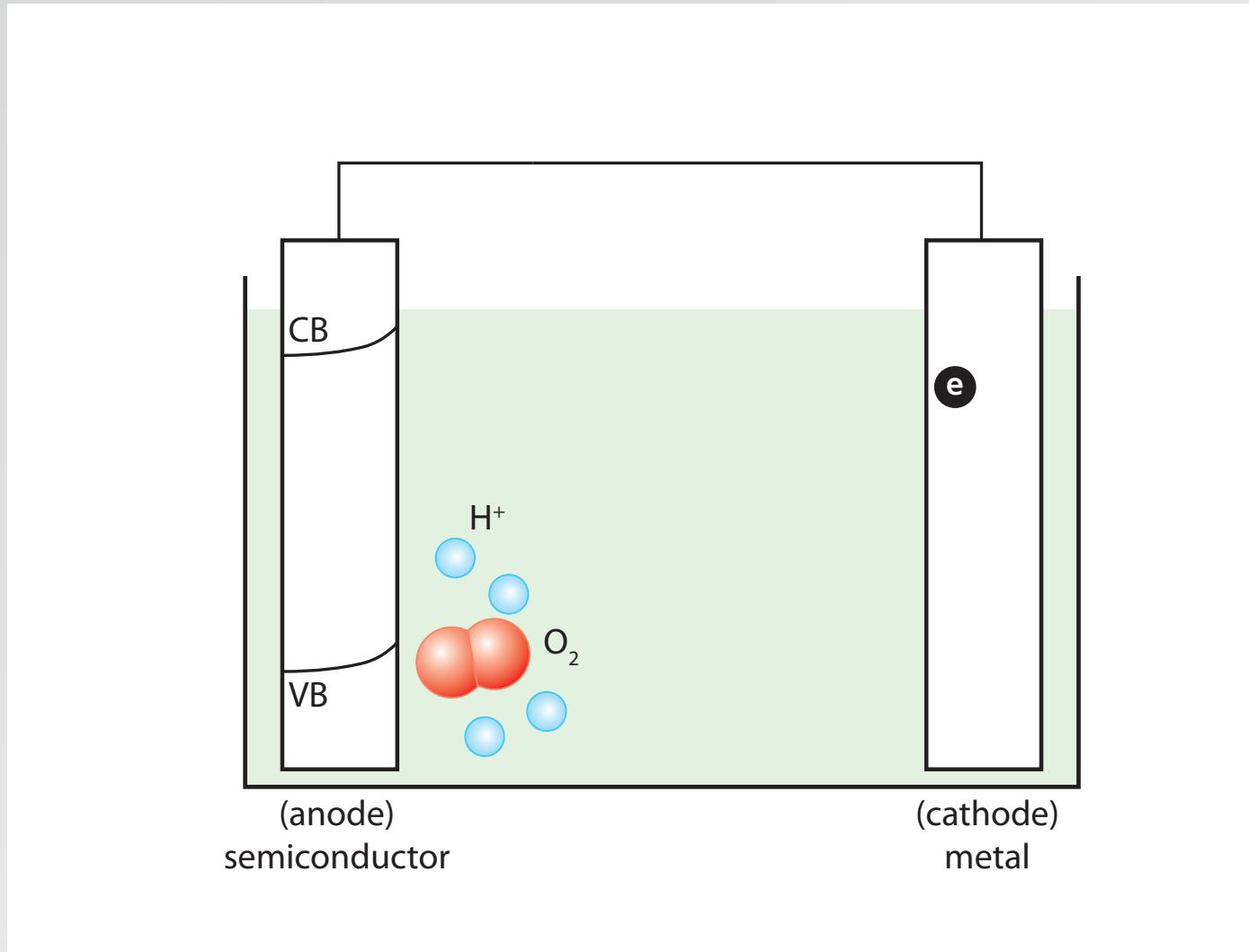


1 properties

2 intermediate band

3 devices

water splitting

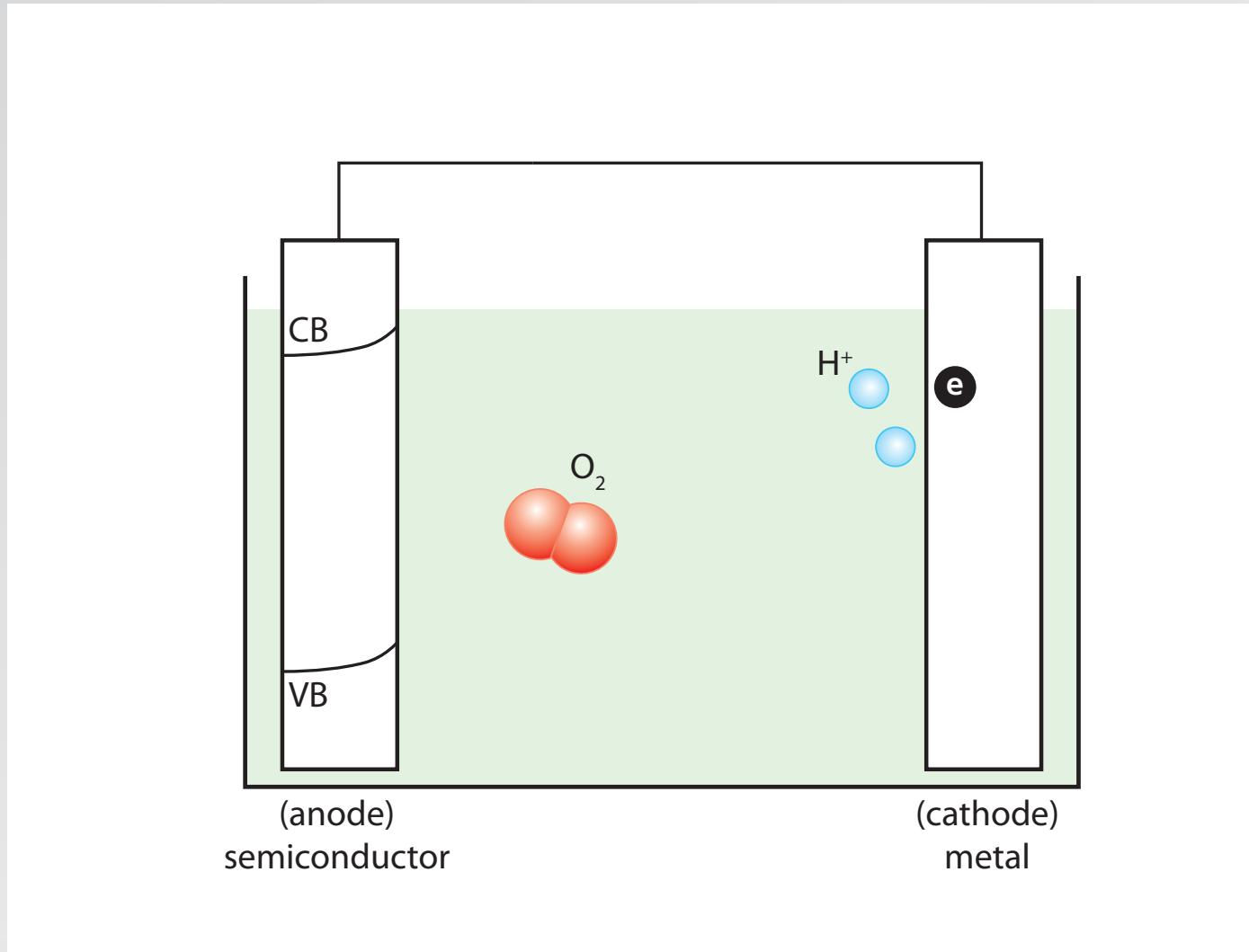


1 properties

2 intermediate band

3 devices

water splitting

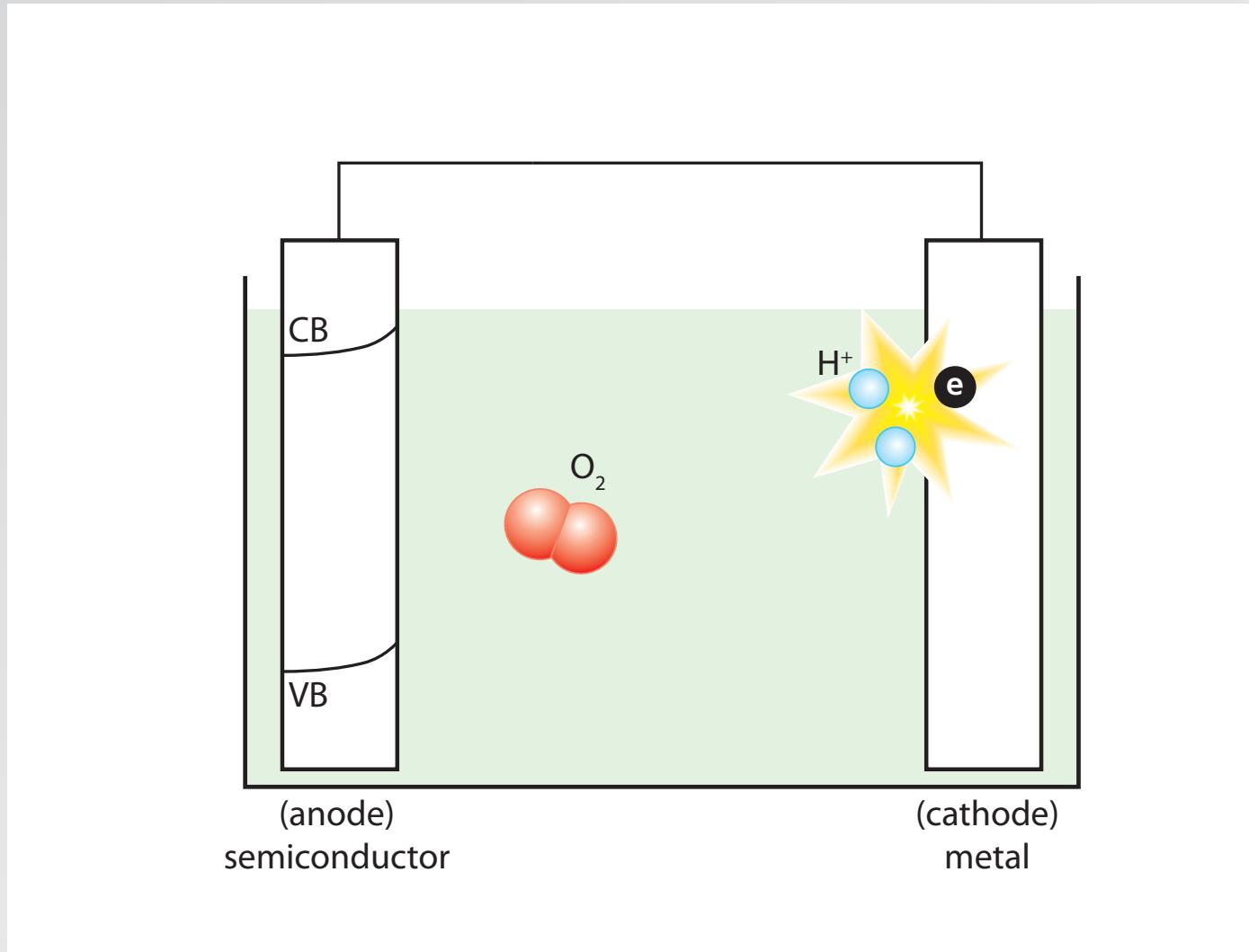


1 properties

2 intermediate band

3 devices

water splitting

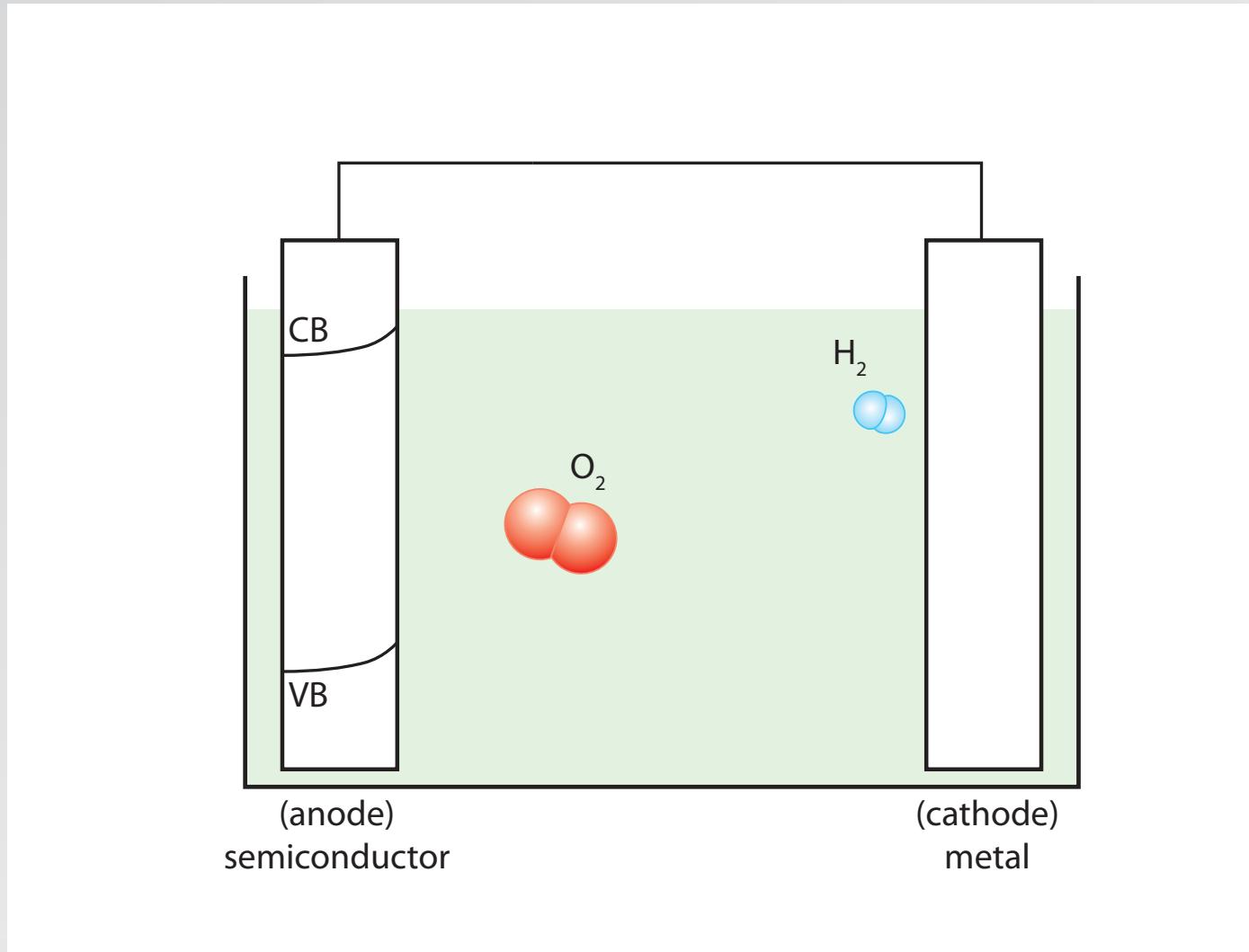


1 properties

2 intermediate band

3 devices

water splitting

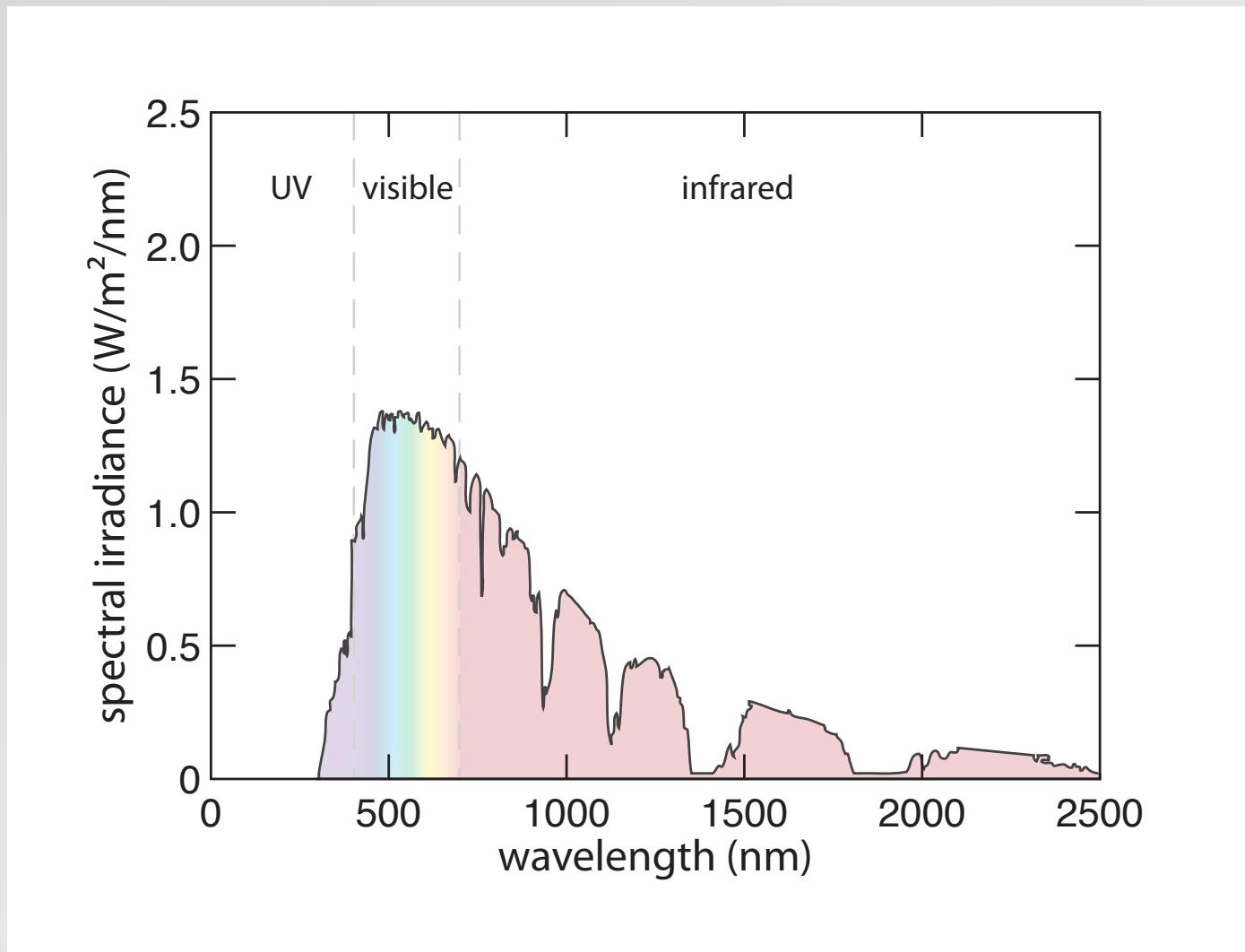


1 properties

2 intermediate band

3 devices

solar radiation spectrum

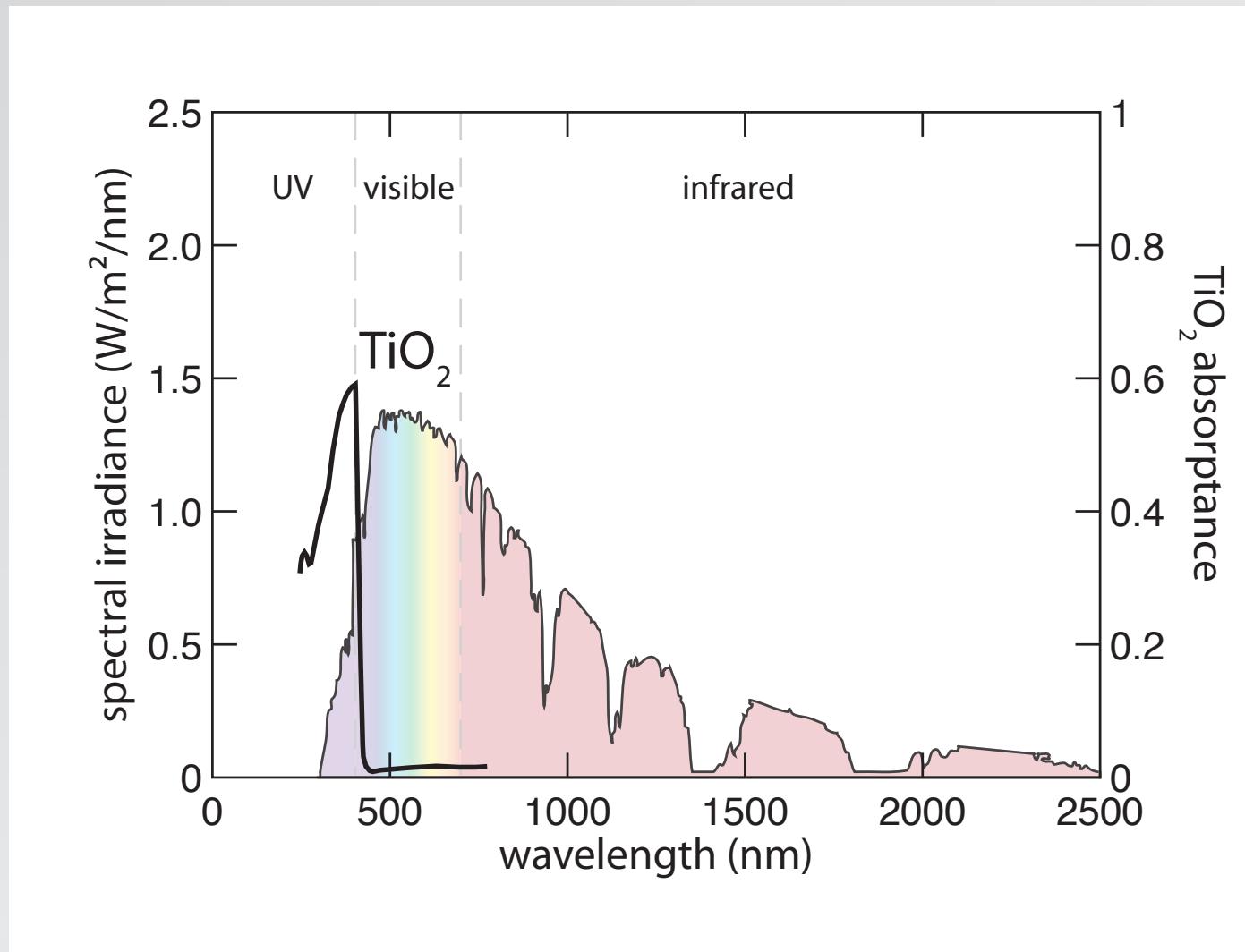


1 properties

2 intermediate band

3 devices

solar radiation spectrum

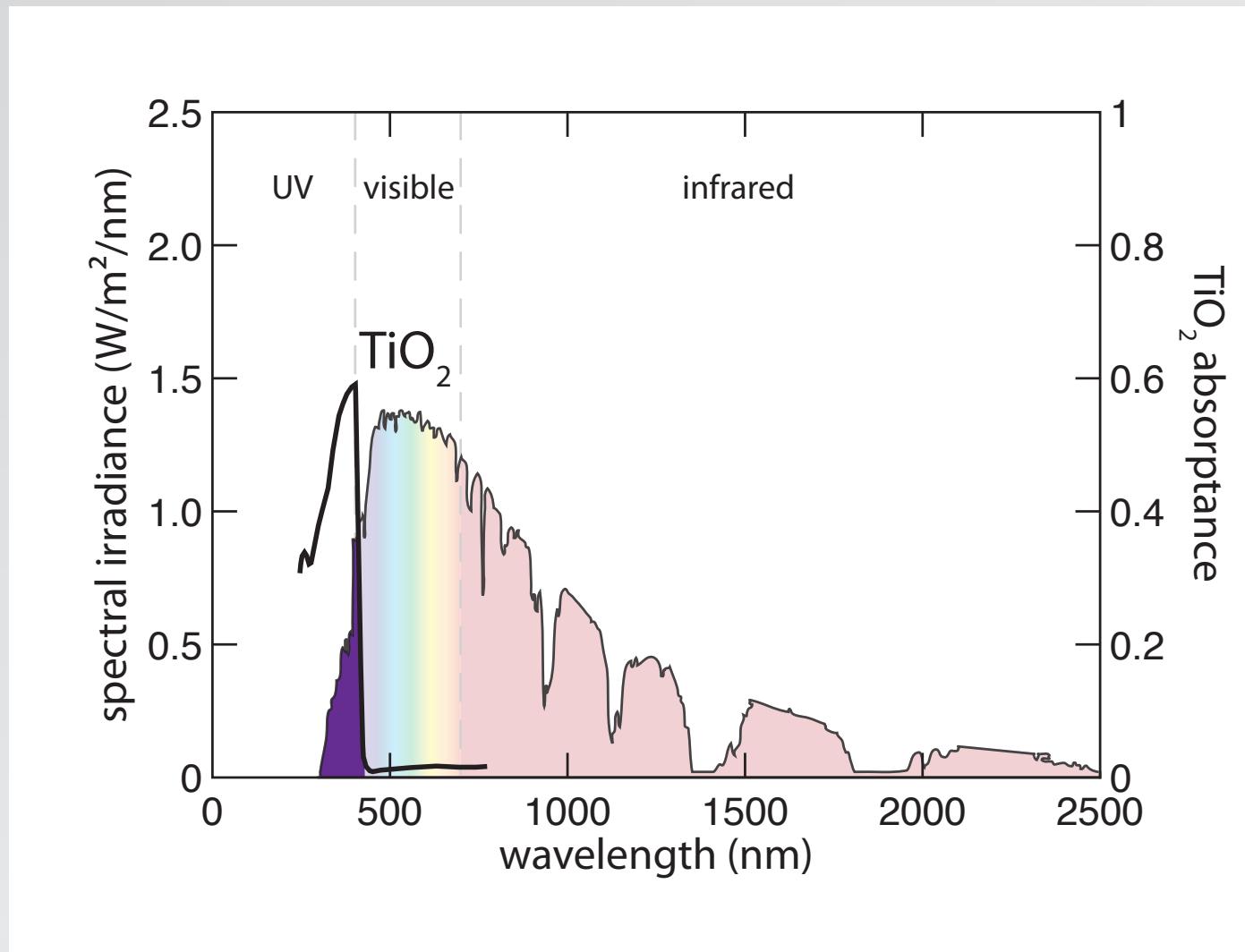


1 properties

2 intermediate band

3 devices

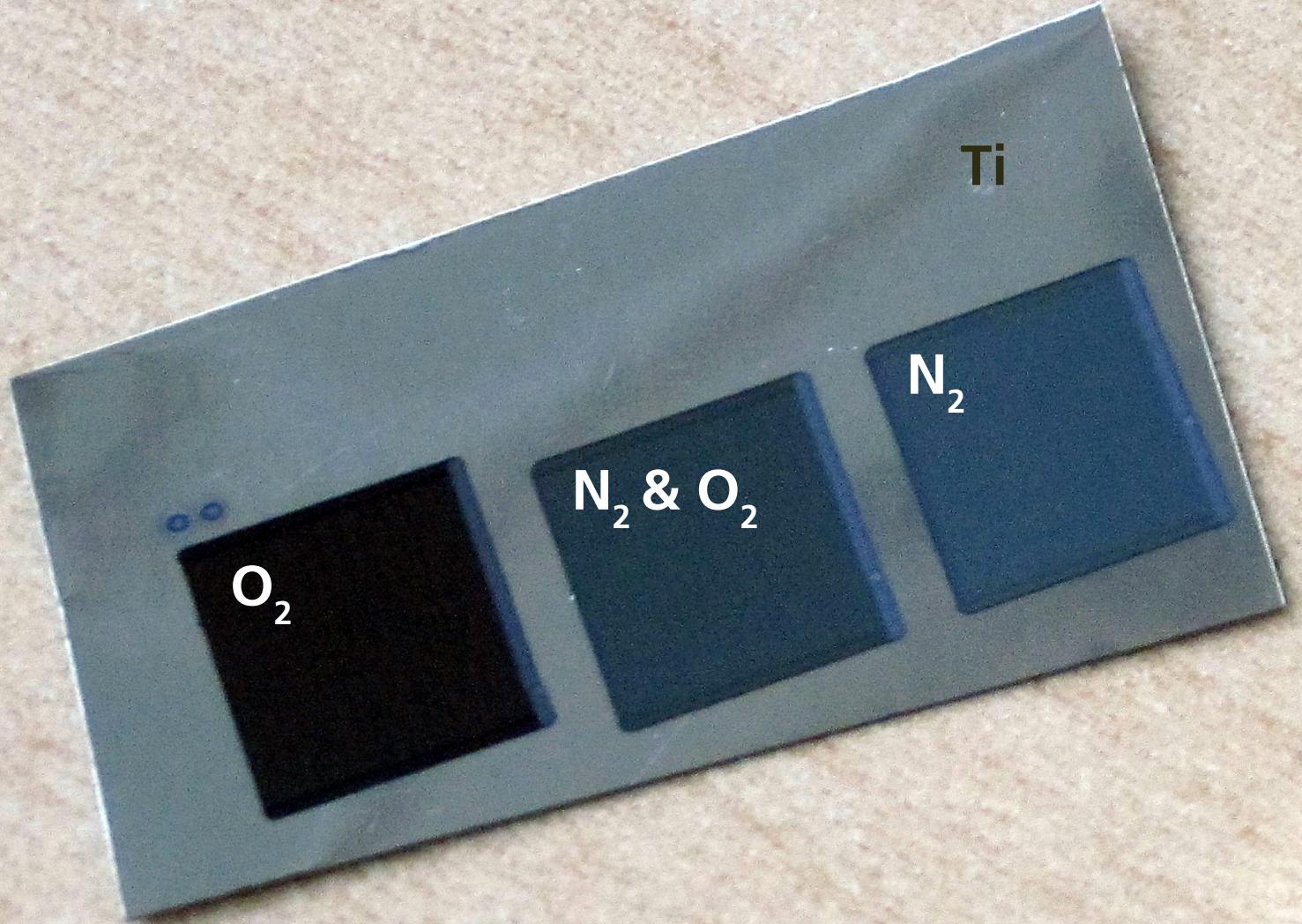
solar radiation spectrum



1 properties

2 intermediate band

3 devices



1 properties

2 intermediate band

3 devices



Things to keep in mind

- can turn b:Si absorption into carrier generation

1 properties

2 intermediate band

3 devices

Things to keep in mind

- can turn b:Si absorption into carrier generation
- very high responsivity in VIS and NIR

1 properties

2 intermediate band

3 devices

Things to keep in mind

- can turn b:Si absorption into carrier generation
- very high responsivity in VIS and NIR
- disruptive improvement in Si imaging

1 properties

2 intermediate band

3 devices

Things to keep in mind

- can turn b:Si absorption into carrier generation
- very high responsivity in VIS and NIR
- disruptive improvement in Si imaging
- potential benefits in solar energy harvesting



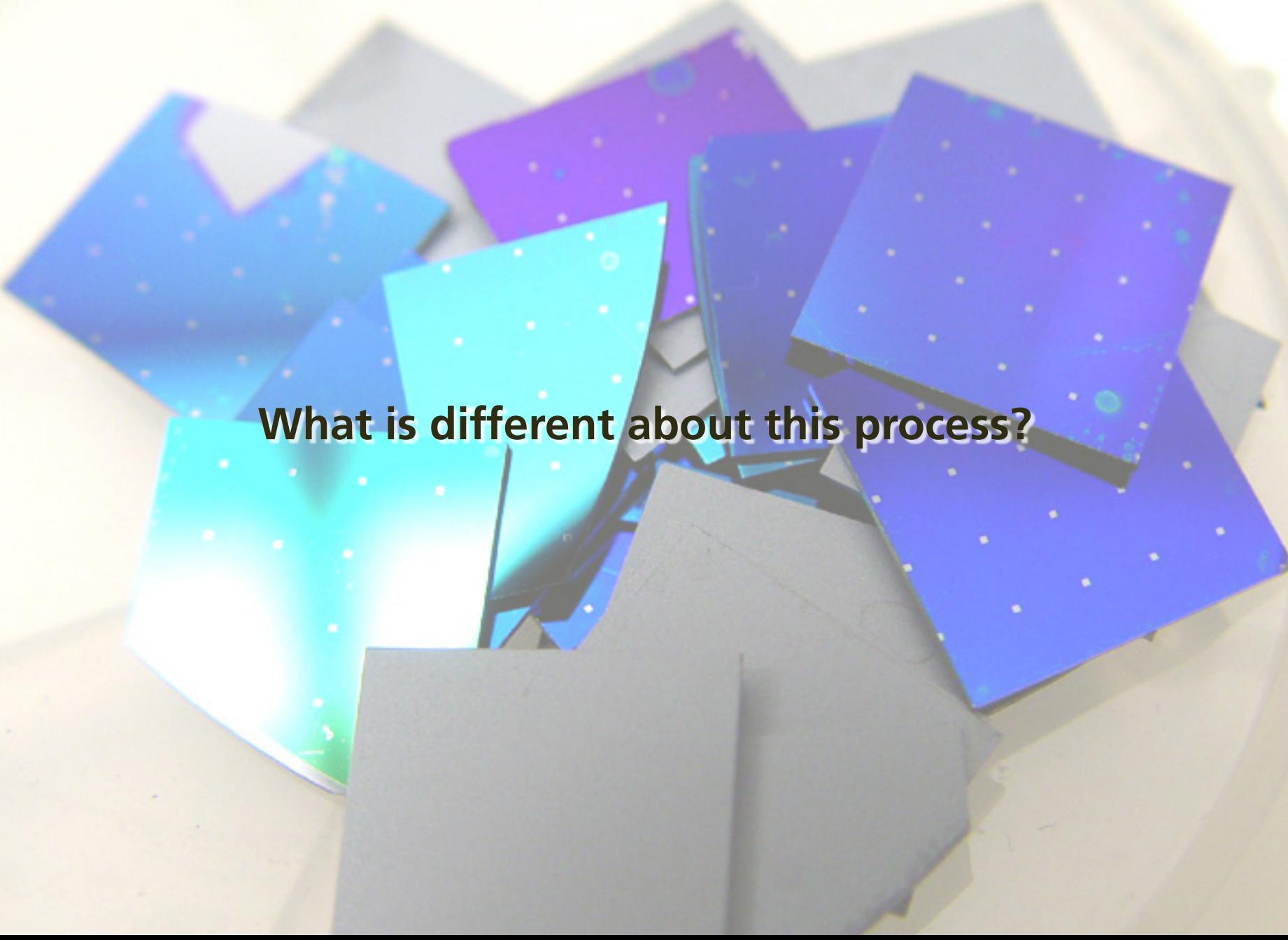
Summary

- new doping process
- new class of material
- new types of devices

1 properties

2 intermediate band

3 devices

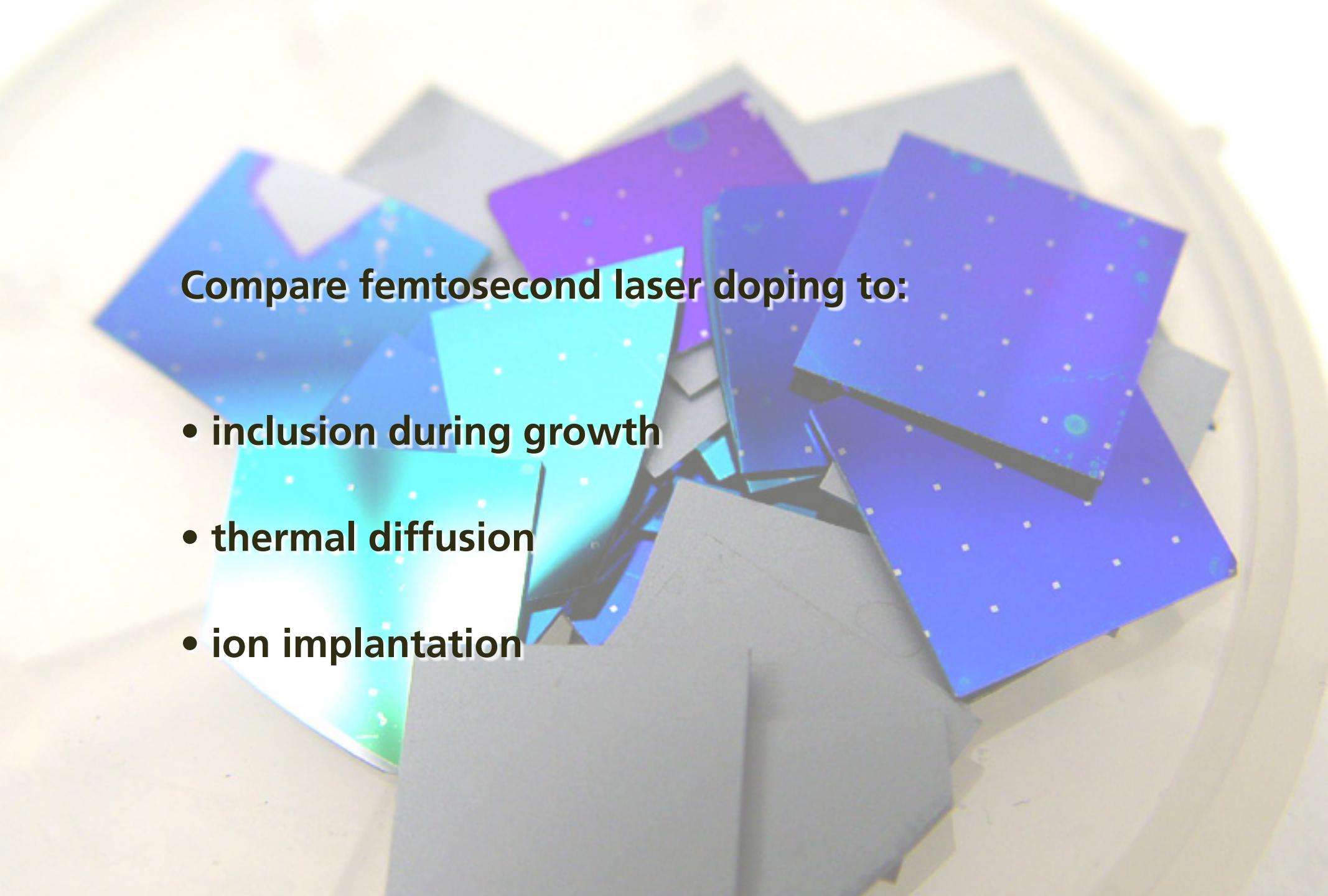


What is different about this process?

1 properties

2 intermediate band

3 devices



Compare femtosecond laser doping to:

- inclusion during growth
- thermal diffusion
- ion implantation

1 properties

2 intermediate band

3 devices





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Army Research Office

DARPA

Department of Energy

NDSEG

National Science Foundation

for more information and a copy of this presentation:

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